
Transistor and IC design for 50GHz and above

Mark Rodwell, UCSB

mm-wave systems:

Prof. U. Madhow & group: UCSB

mm-wave ICs

S-K Kim, R. Maurer, A. Ahmed, H. Yu, H-C. Park, T. Reed, UCSB

Prof. J. Buckwalter & group, UCSB

J. Hacker, Z. Griffith: Teledyne Scientific and Imaging

M. Seo: Sungkyunkwan University

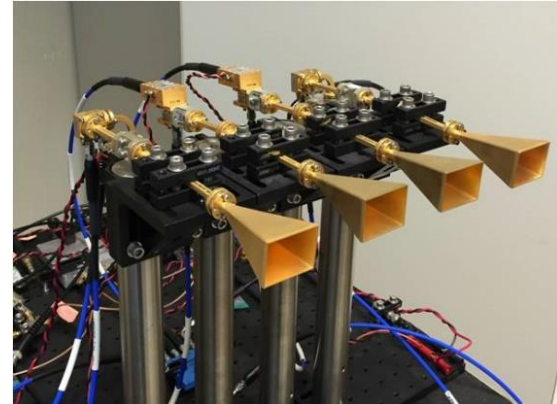
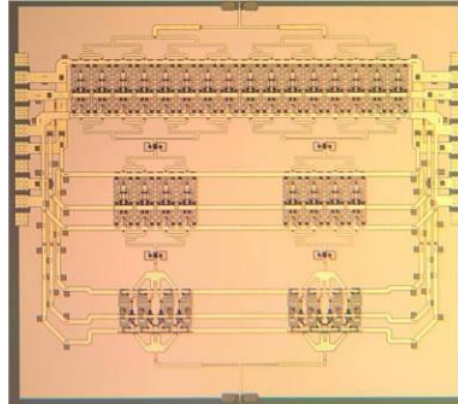
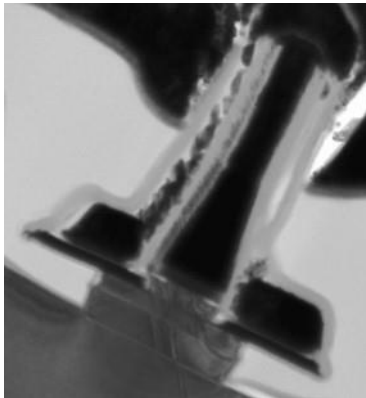
mm-Wave Transistors :

J. Rode, P. Choudhary, B. Markman, Y. Fang, J. Wu,

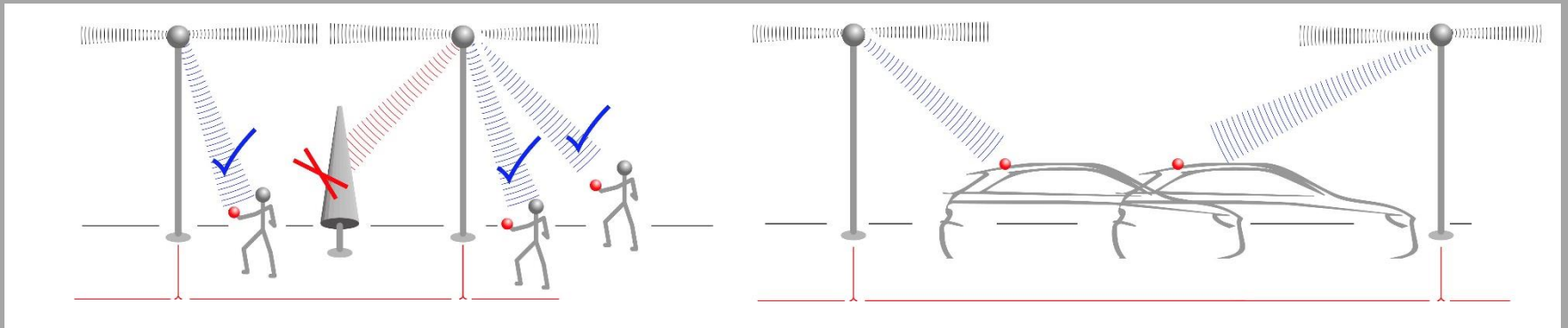
A.C. Gossard, B. Thibeault, W. Mitchell: UCSB

M. Urteaga, B. Brar: Teledyne Scientific and Imaging

Why mm-wave wireless ?

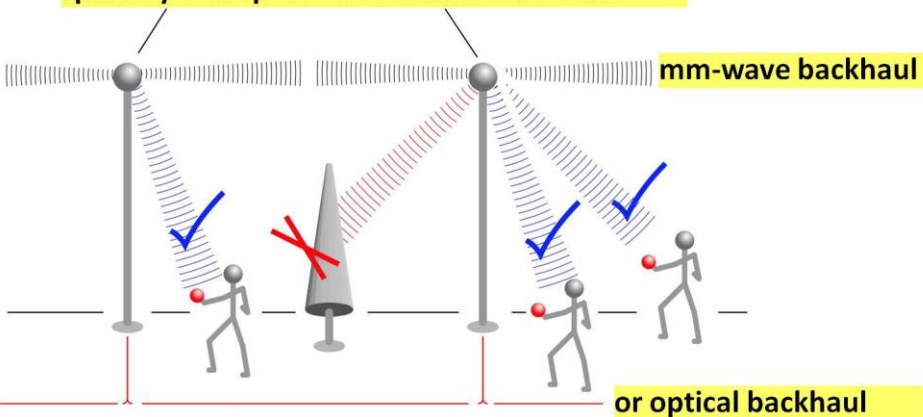


Overview

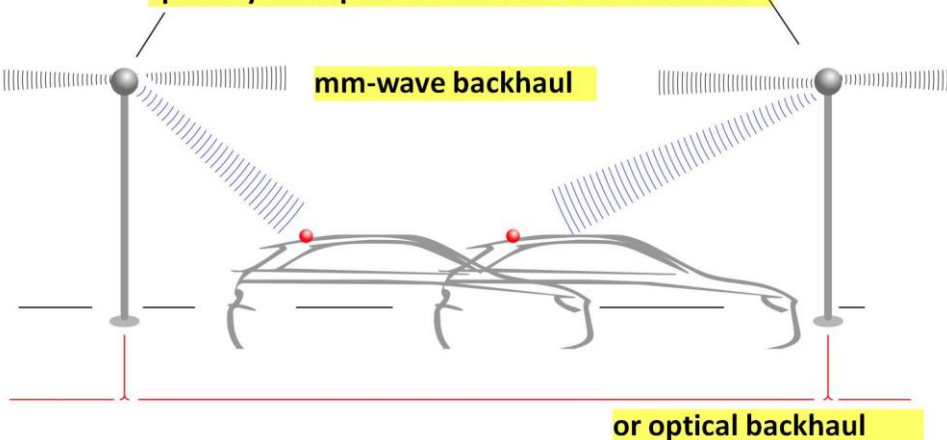


mm-Waves: high-capacity mobile communications

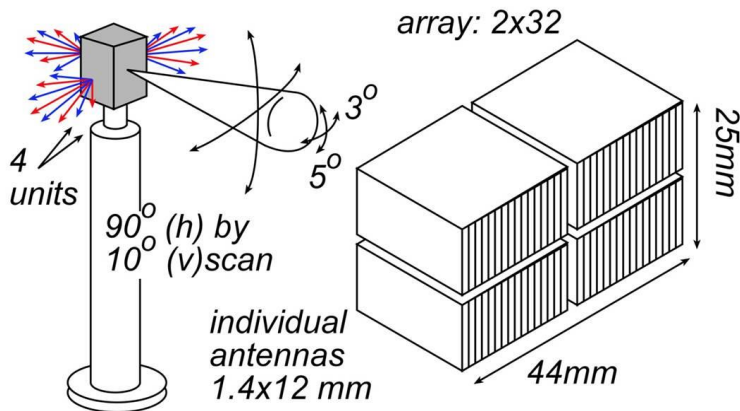
spatially-multiplexed mm-wave base stations



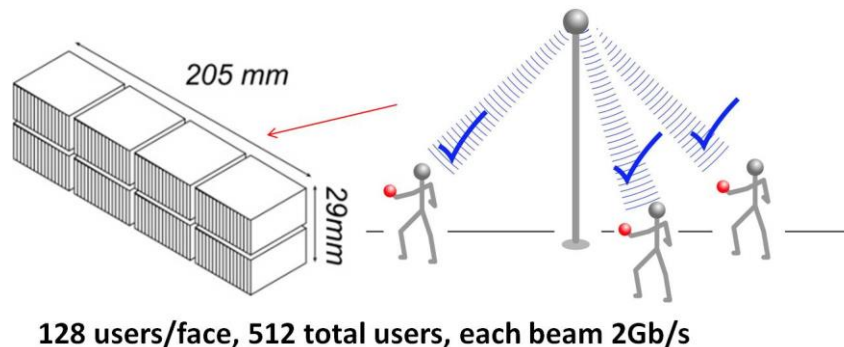
spatially-multiplexed mm-wave base stations



140 GHz, 10 Gb/s Adaptive Picocell Backhaul



60 GHz, 1 Tb/s Spatially-Multiplexed Base Station



128 users/face, 512 total users, each beam 2Gb/s

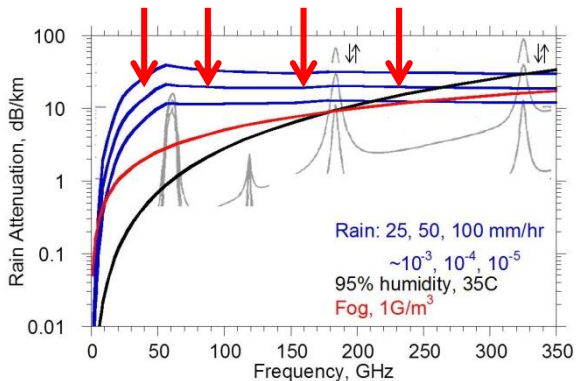
Needs → research:

RF front end: phased array ICs, high-power transmitters, low-noise receivers

IF/baseband: ICs for multi-beam beamforming, for ISI/multipath suppression, ...

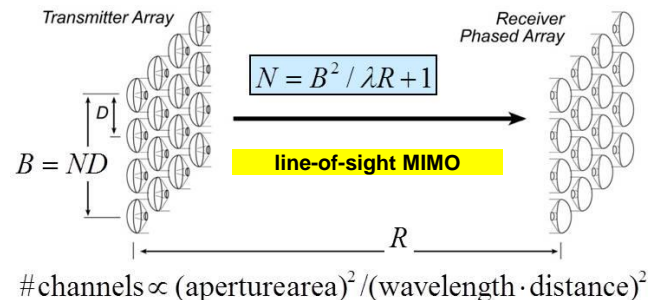
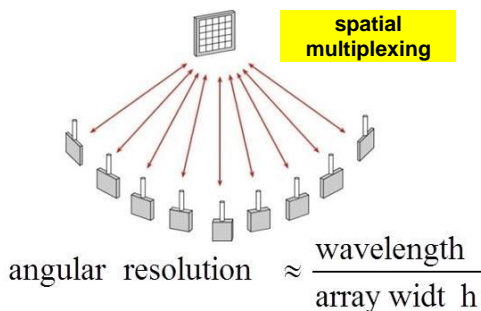
mm-Waves: benefits & challenges

Large available spectrum

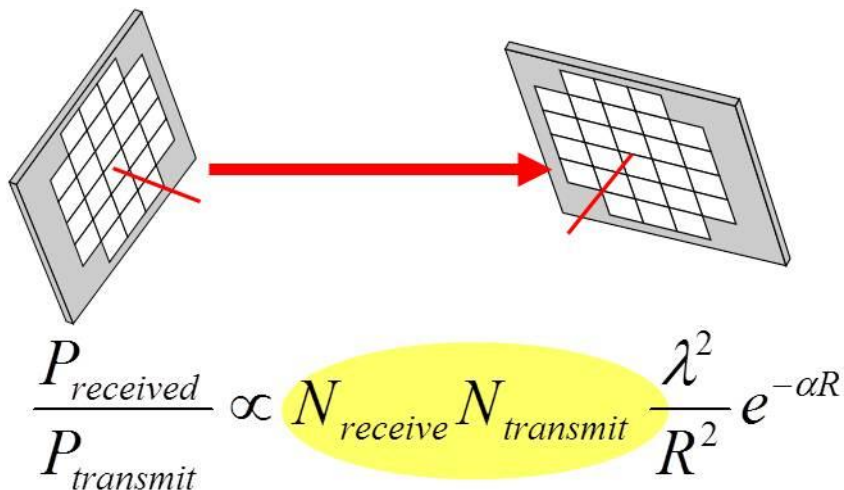


(note high attenuation in foul weather)

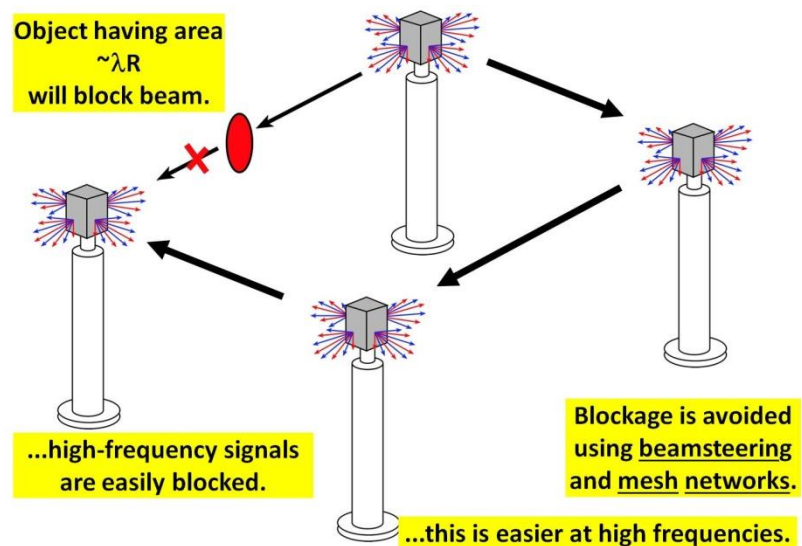
Massive # parallel channels



Need phased arrays (overcome high attenuation)

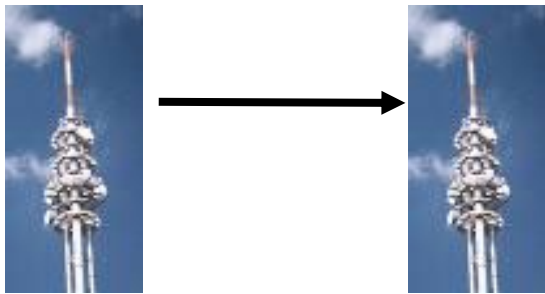


Need mesh networks



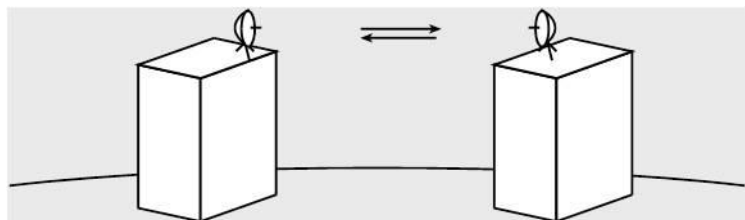
mm-Wave Wireless Needs Phased Arrays

isotropic antenna → weak signal → short range



$$\left(\frac{P_{received}}{P_{transmitted}} \right) \propto \left(\frac{\lambda^2}{R^2} \right) e^{-\alpha R}$$

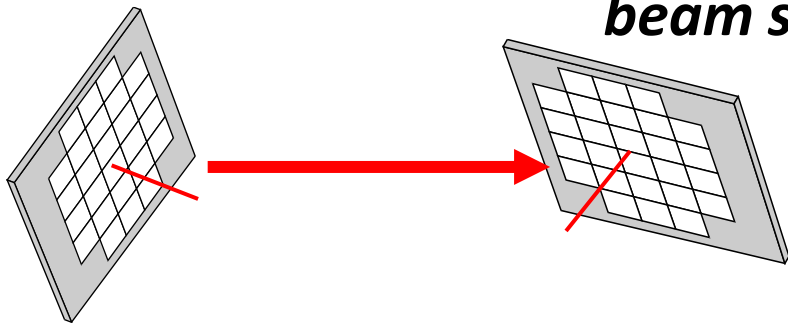
highly directional antenna → strong signal, but must be aimed



$$\left(\frac{P_{received}}{P_{transmitted}} \right) \propto D_t D_r \left(\frac{\lambda^2}{R^2} \right) e^{-\alpha R}$$

*no good for mobile
must be precisely aimed → too expensive for telecom operators*

beam steering arrays → strong signal, steerable

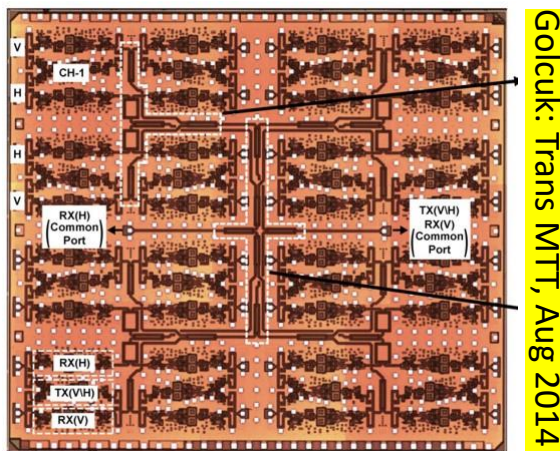
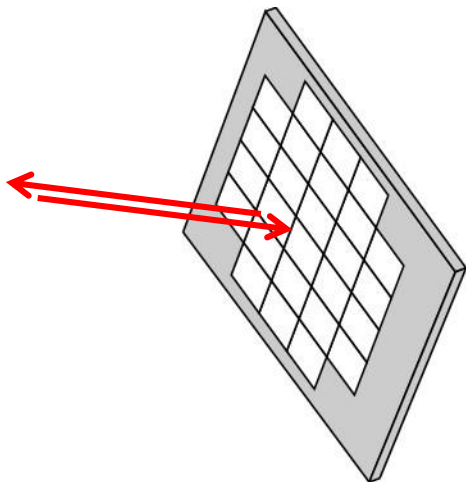


$$\frac{P_{received}}{P_{transmit}} \propto N_{receive} N_{transmit} \frac{\lambda^2}{R^2} e^{-\alpha R}$$

32-element array → 30 (45?) dB increased SNR

Millimeter-wave imaging

10,000-pixel, 94GHz imaging array → 10,000 elements



Demonstrated:

SiGe (UCSD/Rebeiz)

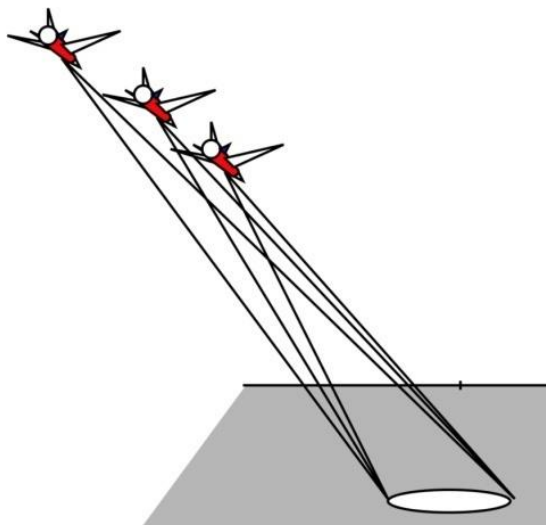
~1.3kW: 10,000 elements

Lower-power designs:

InP, CMOS, SiGe

(UCSB, UCSD, Virginia Poly.)

235 GHz video-rate synthetic aperture radar



1 transmitter, 1 receiver

100,000 pixels

20 Hz refresh rate

5 cm resolution @ 1km

50 Watt transmitter

(tube, solid-state driver)

mm-wave imaging radar: TV-like resolution

mm-waves → high resolution from small apertures

What you see in fog



What 10GHz radar shows

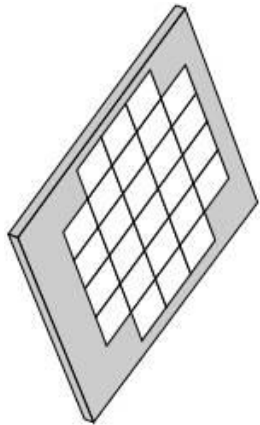


What you want to see



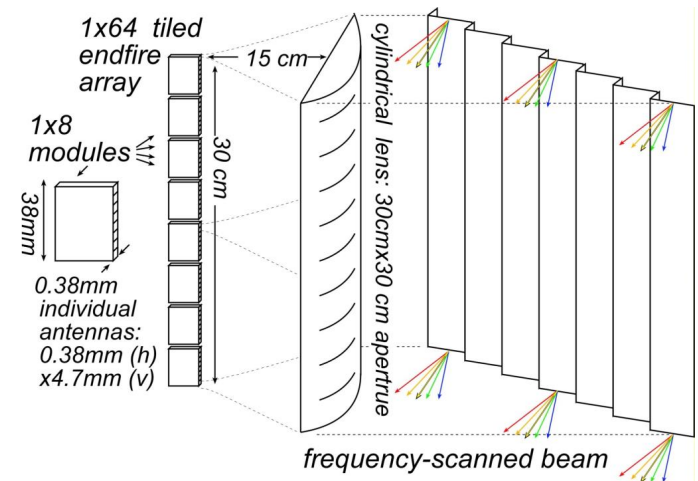
goal: ~0.2° resolution, 10³-10⁶ pixels

Large NxN phased array

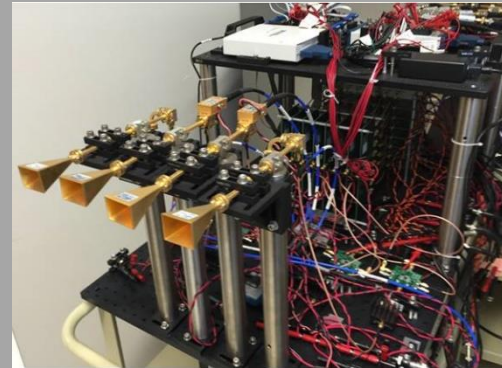
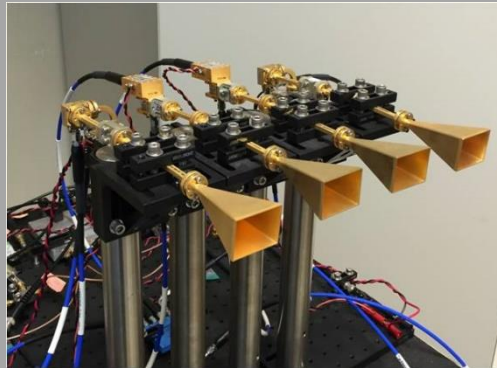


ultimate: ~400 GHz; intermediate: ~140 GHz

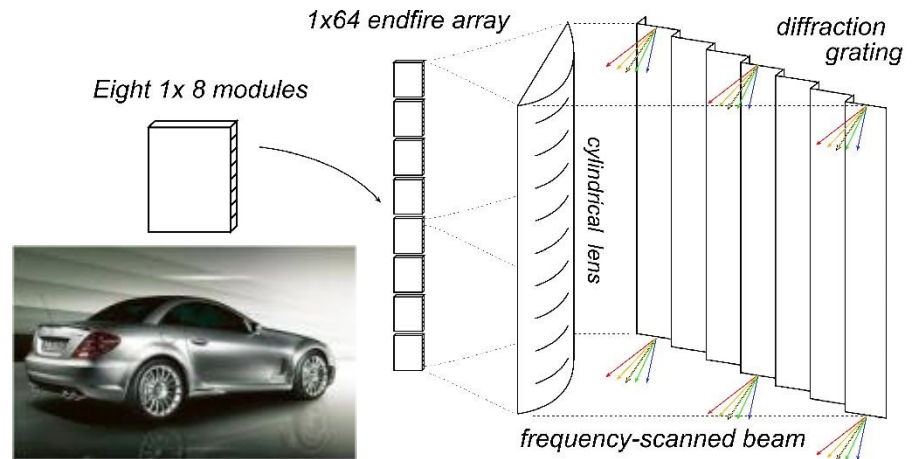
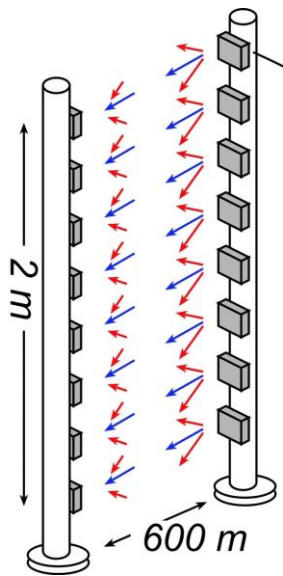
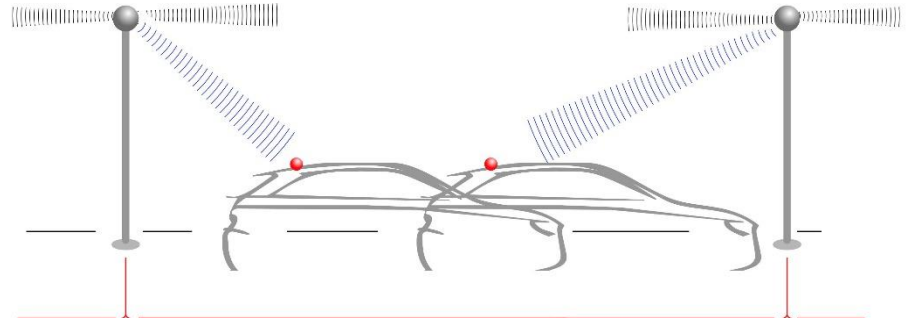
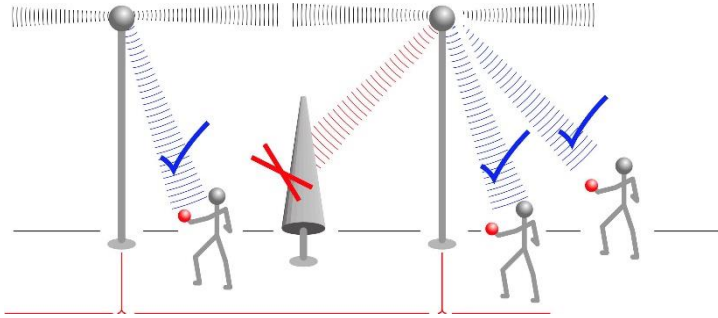
Frequency-scanned 1xN array



mm-wave systems



Target Systems



arrays

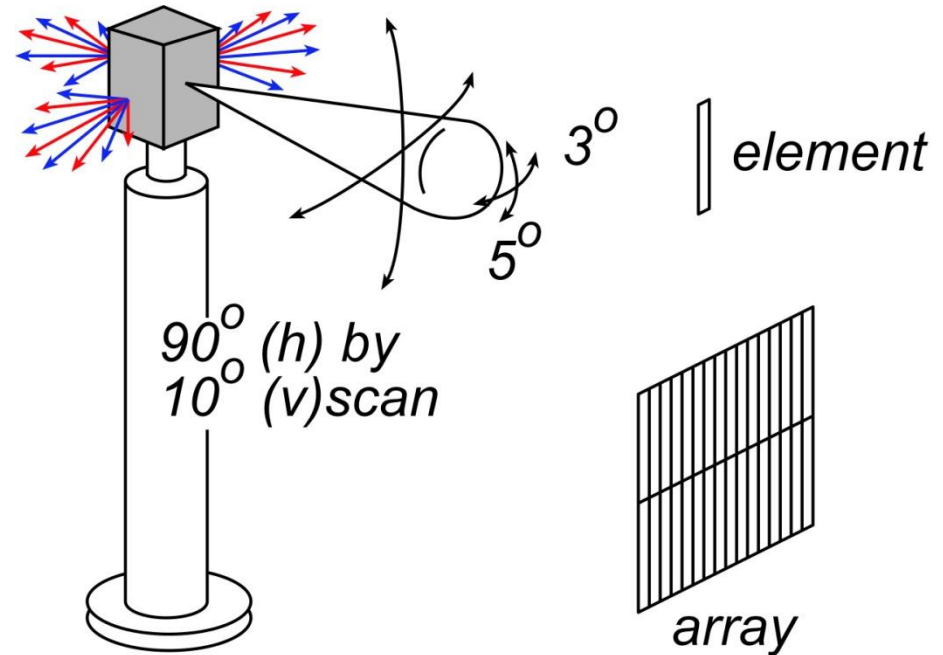
Antenna & array basics

Overall array sets beamwidth and gain

$$\text{horizontal beamwidth} \cong \frac{\lambda}{\text{array width } h} \text{ (radians)}$$

$$\text{vertical beamwidth} \cong \frac{\lambda}{\text{array height}}$$

$$\text{Gain (directivity)} \cong \frac{4\pi \cdot \text{array area}}{\lambda^2}$$



Individual element sets maximum beamsteering range.

$$\text{horizontal steering} \cong \frac{\lambda}{\text{element width}} \text{ (radians)}$$

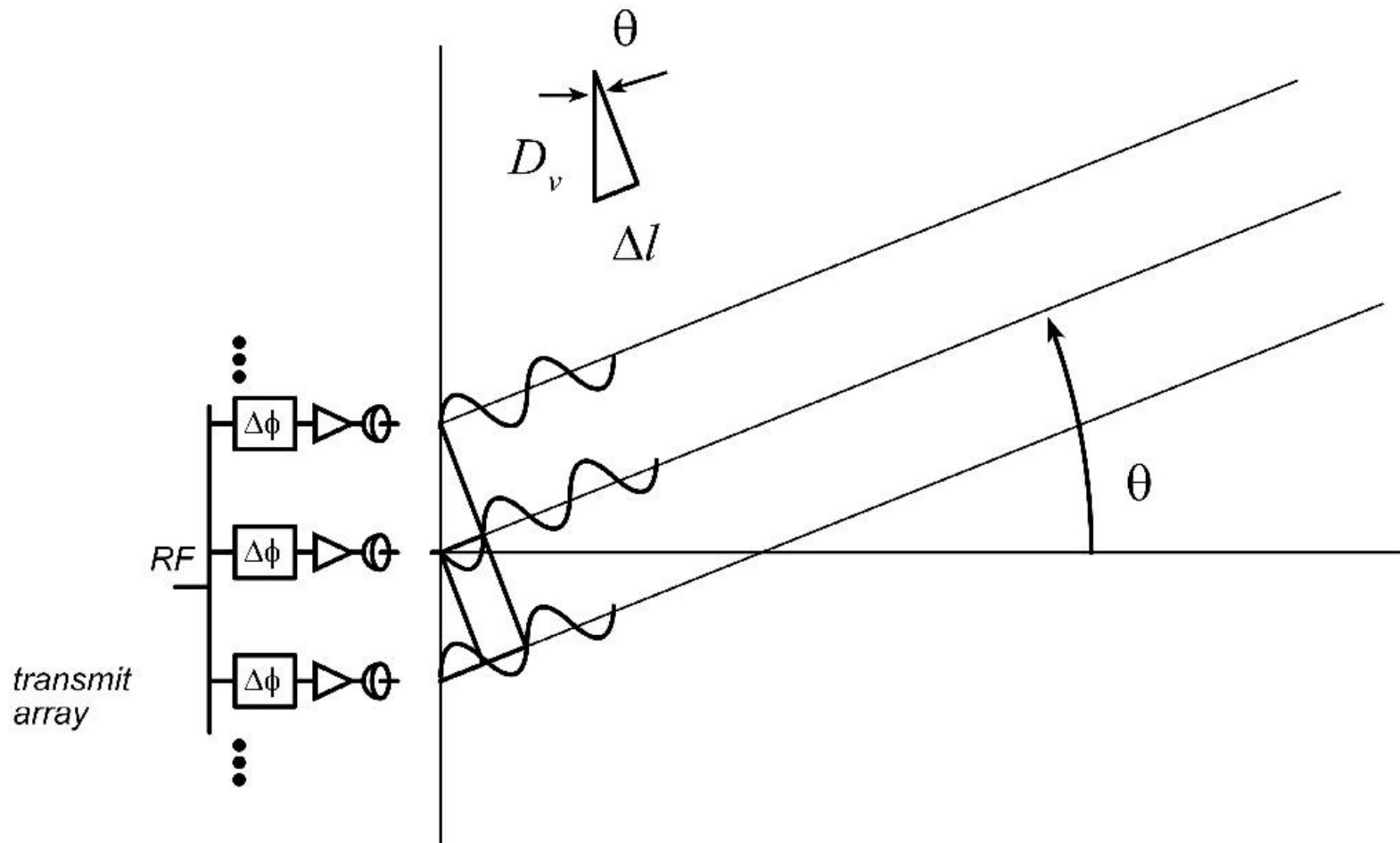
$$\text{vertical steering} \cong \frac{\lambda}{\text{element height}}$$

Electronic Beamsteering, a.k.a. phased array

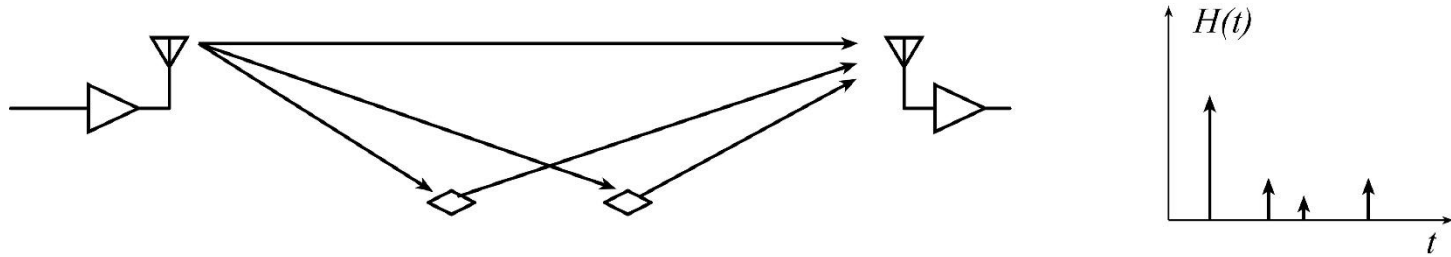
Phase - shifters bring signals back into phase at physical angle θ .

Path length difference $\Delta l = D_v \sin \theta$

Required electrical phase shift between adjacent elements $\Delta\phi = 2\pi \cdot \Delta l / \lambda$.



Reminder: Multipath Propagation



Given large angular beamwidth (low - directivity antennas)

Many objects in antenna beam pattern.

Many signal paths : multi - path propagation

Each path has different length, different delay.

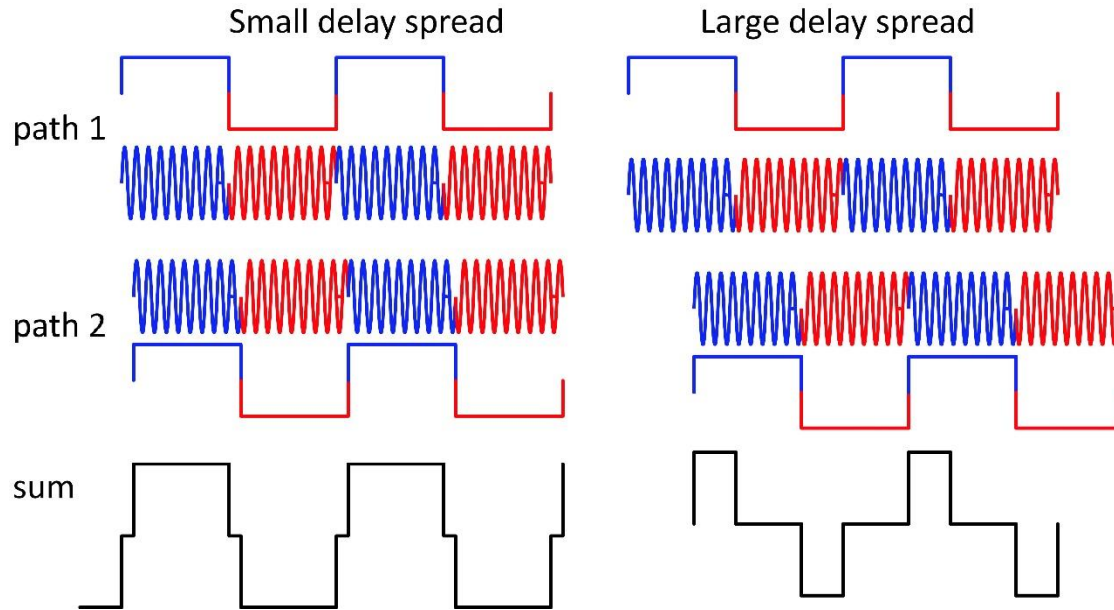
Reflecting surface boundary condition : possible phase shift.

Each path has different signal strength

- Directivity of antennas

- Strength of reflection

Fading vs Intersymbol interference



(Delay spread \ll Symbol period) \rightarrow Fading

LOS and NLOS signals arrive with symbol periods \sim aligned

Carriers are out of phase \rightarrow interference \rightarrow possibly very weak signal

fix : two receiving antennas at appropriate separation

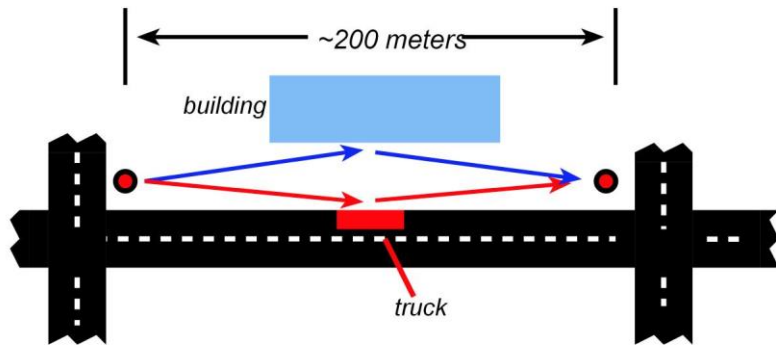
(Delay spread $>$ Symbol period) \rightarrow Intersymbol interference

One bit period interferes with another

need adaptive equalizer in receiver

or use OFDM : longer symbol periods

Beamforming can suppress ISI

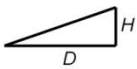
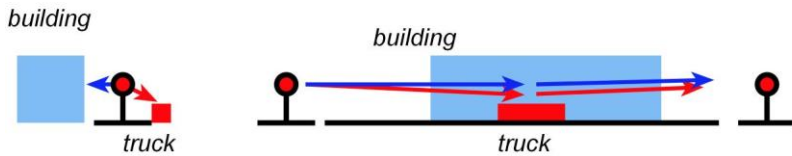


1 Gbaud with 10° array beamwidth :
multipath mostly causes fading
not much ISI

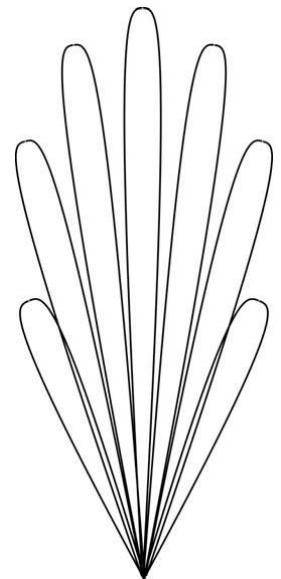
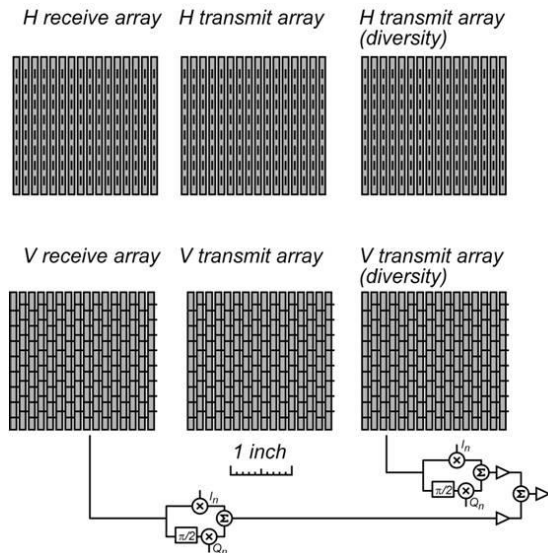
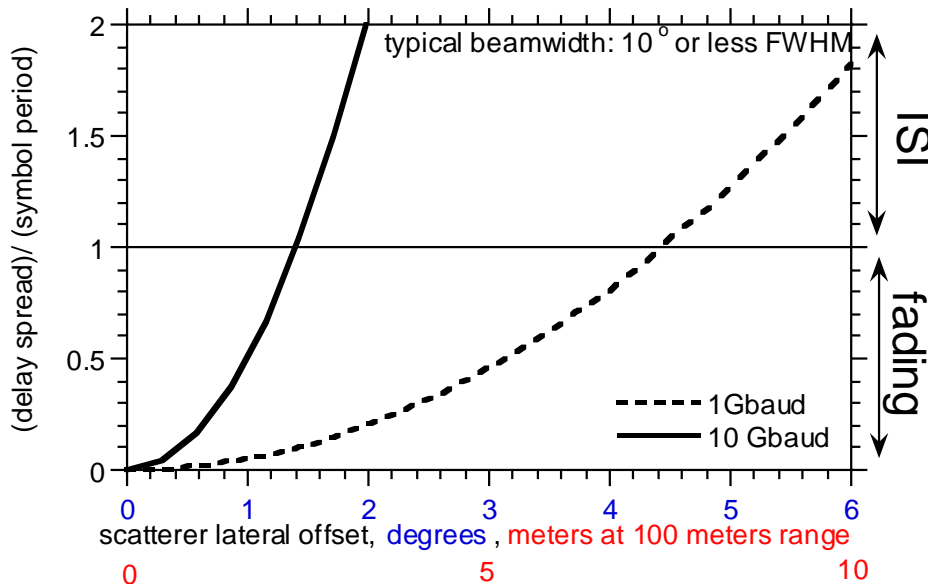
10 Gbaud with 10° array beamwidth :
significant fading and significant ISI

Solution 1: larger arrays
narrower beamwidth

Solution 2: multiple arrays
multiple receivers to handle fading ?
can sum these to form narrow nulls!
also handles fading and ISI



$$\text{Delay spread} \cong \frac{H^2}{2Dc}$$

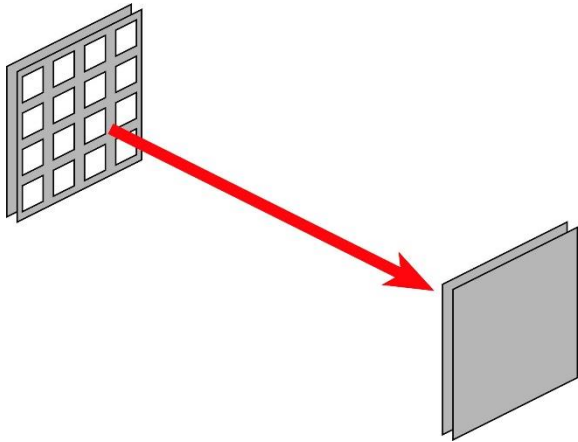


Optimum array size for low system power

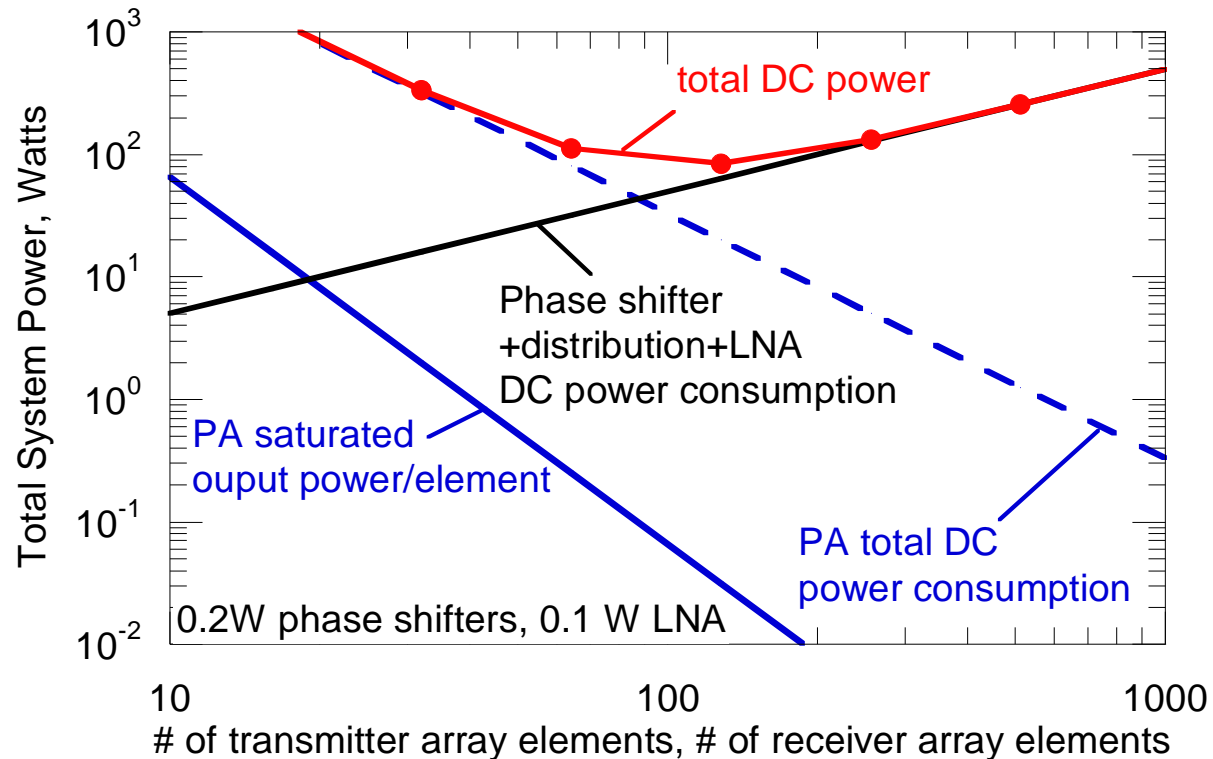
$$\frac{P_{receive}}{P_{transmit}} \propto N^2 \frac{\lambda^2}{R^2} \longrightarrow P_{transmit} \propto \frac{1}{N^2}$$

Do large arrays save power?

$$\text{Total system power} = \frac{P_{transmit}}{\text{efficiency}} + N(\text{power of LNA, phase shifters...})$$

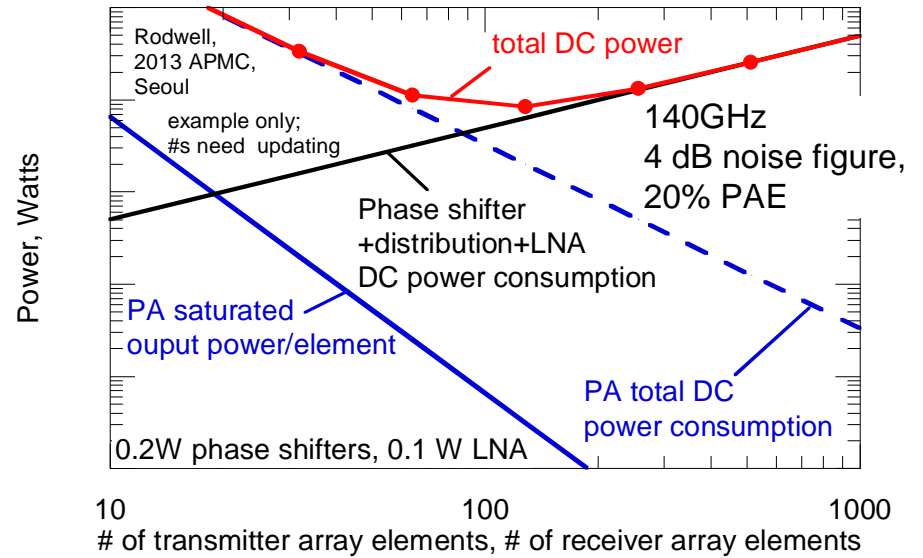
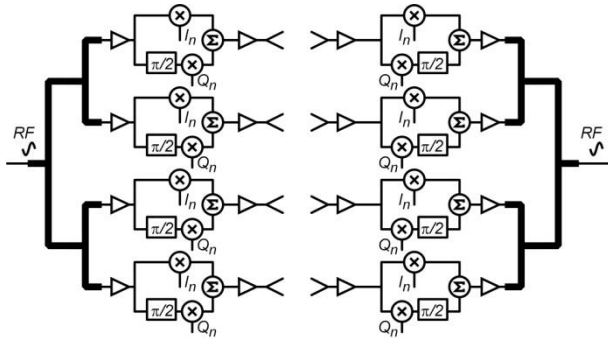
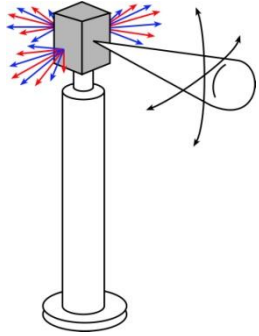


At optimum-size array, target PA output power is typically 10-200 mW

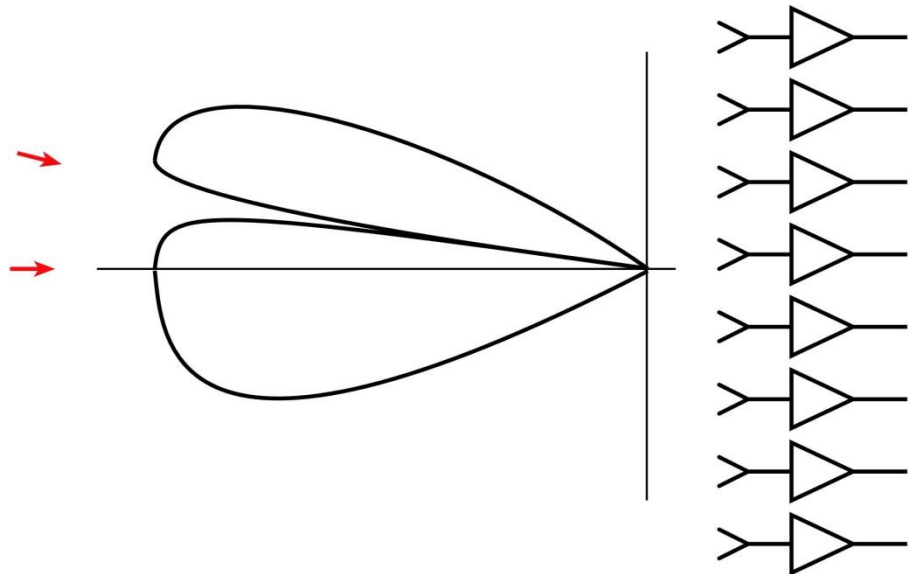
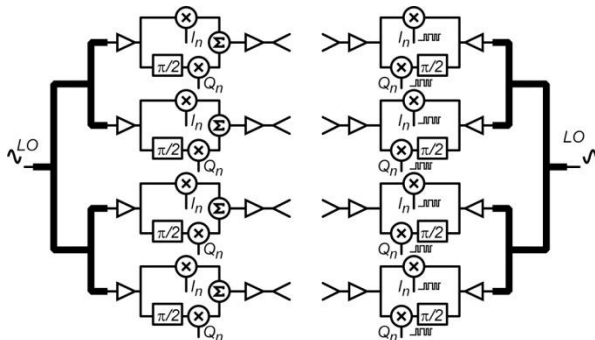


How big should be the array ?

Large arrays:
 more directive \rightarrow less PA power needed
 more channels \rightarrow cost, DC power



Large arrays:
 more directive \rightarrow
 less SNR loss with NLOS nulling
eases multipath equalization

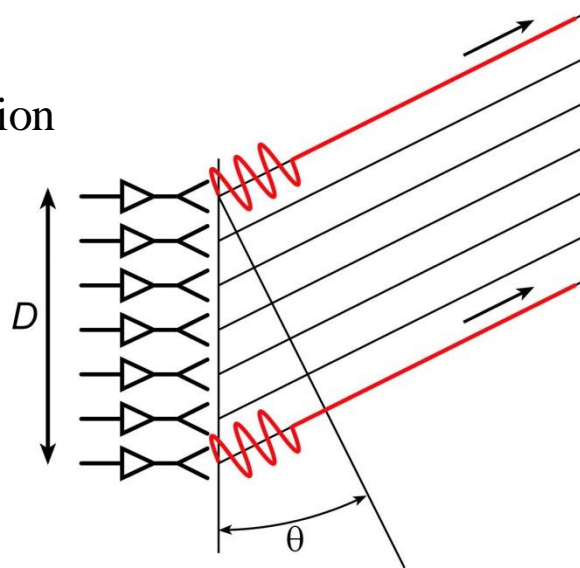


Data delay equalization in large arrays

Simple arrays retime the carrier but not the modulation

$$\text{timing skew} = \frac{D \sin \theta}{c}; \text{ must be below } \sim T_{\text{symbol}} / 2$$

$$\rightarrow \text{bandwidth} \approx \frac{c}{D \sin \theta}$$

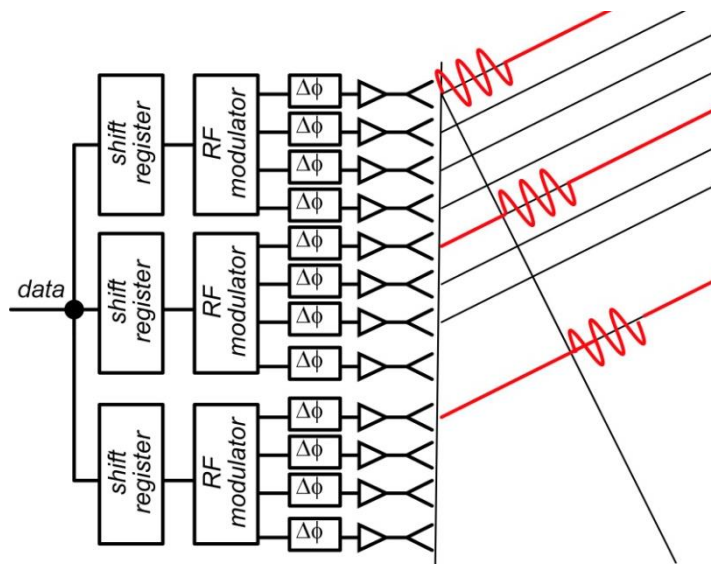


Very large arrays :

compensate by *array tiling*

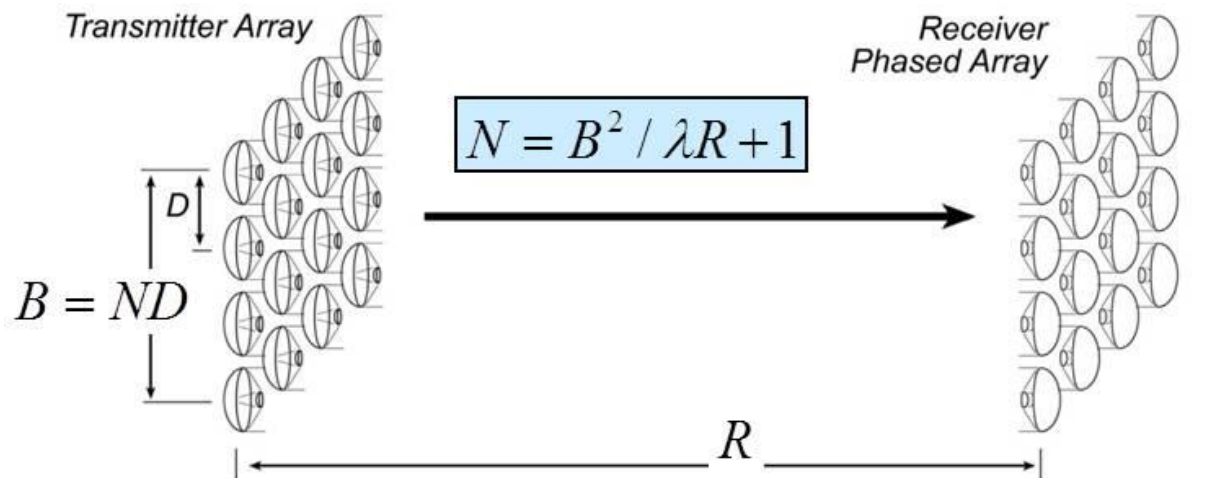
with modulation retimed

between tiles

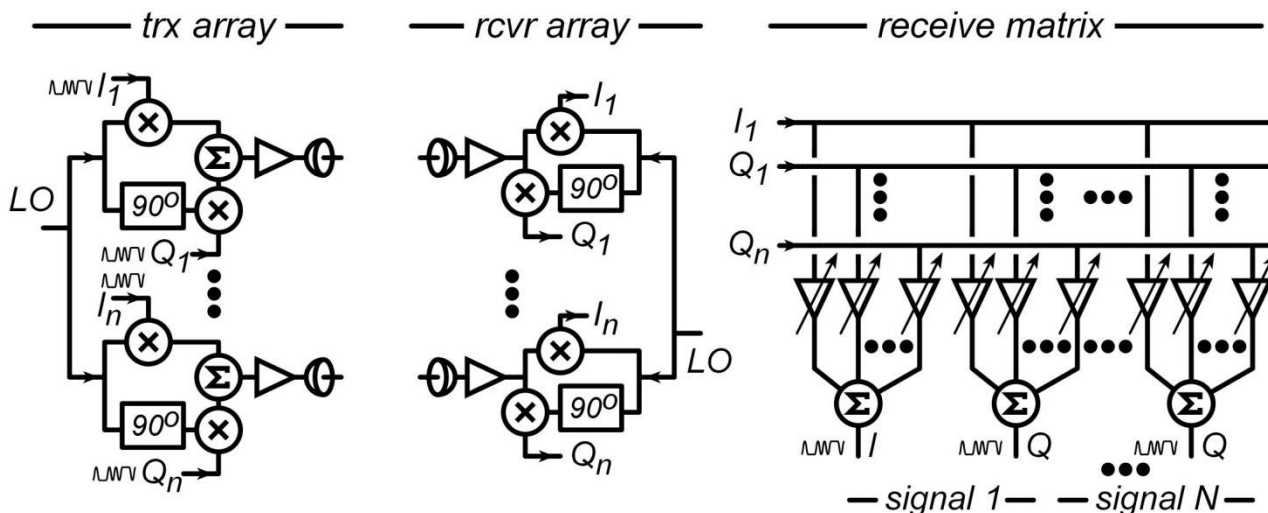
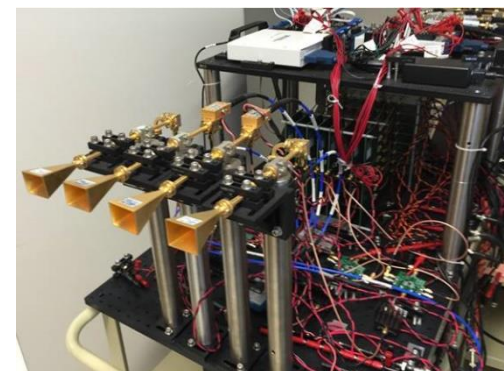
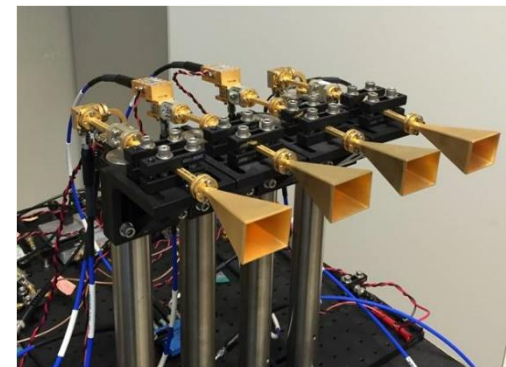


systems

mm-Wave LOS MIMO: multi-channel for high capacity



#channels \propto (aperture area)² / (wavelength · distance)²



Torklinson : 2006 Allerton Conference
 Sheldon : 2010 IEEE APS-URSI
 Torklinson : 2011 IEEE Trans Wireless Comm.

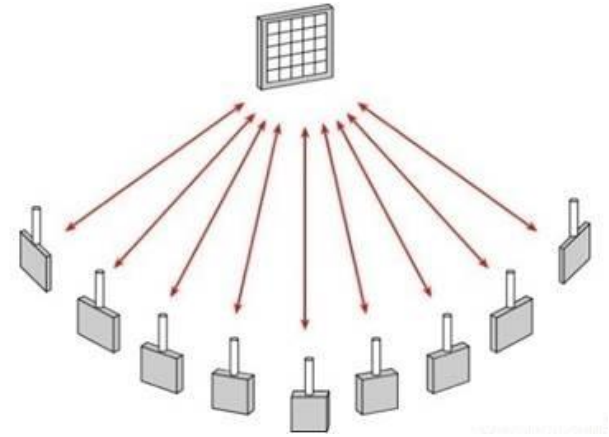
Spatial Multiplexing: massive capacity RF networks

multiple independent beams

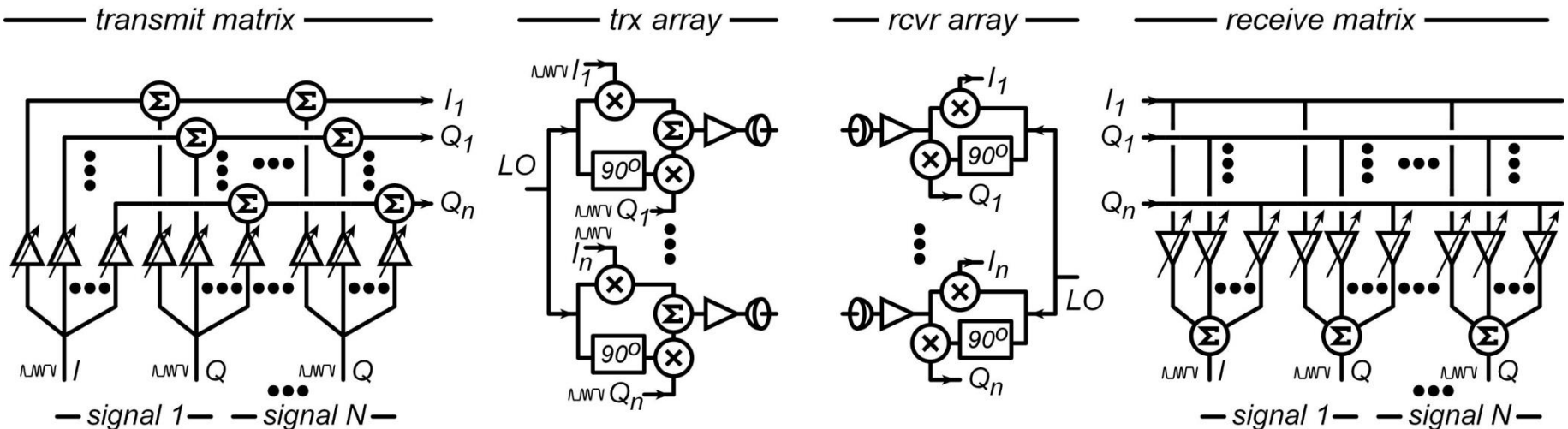
each carrying different data

each independently aimed

beams = # array elements

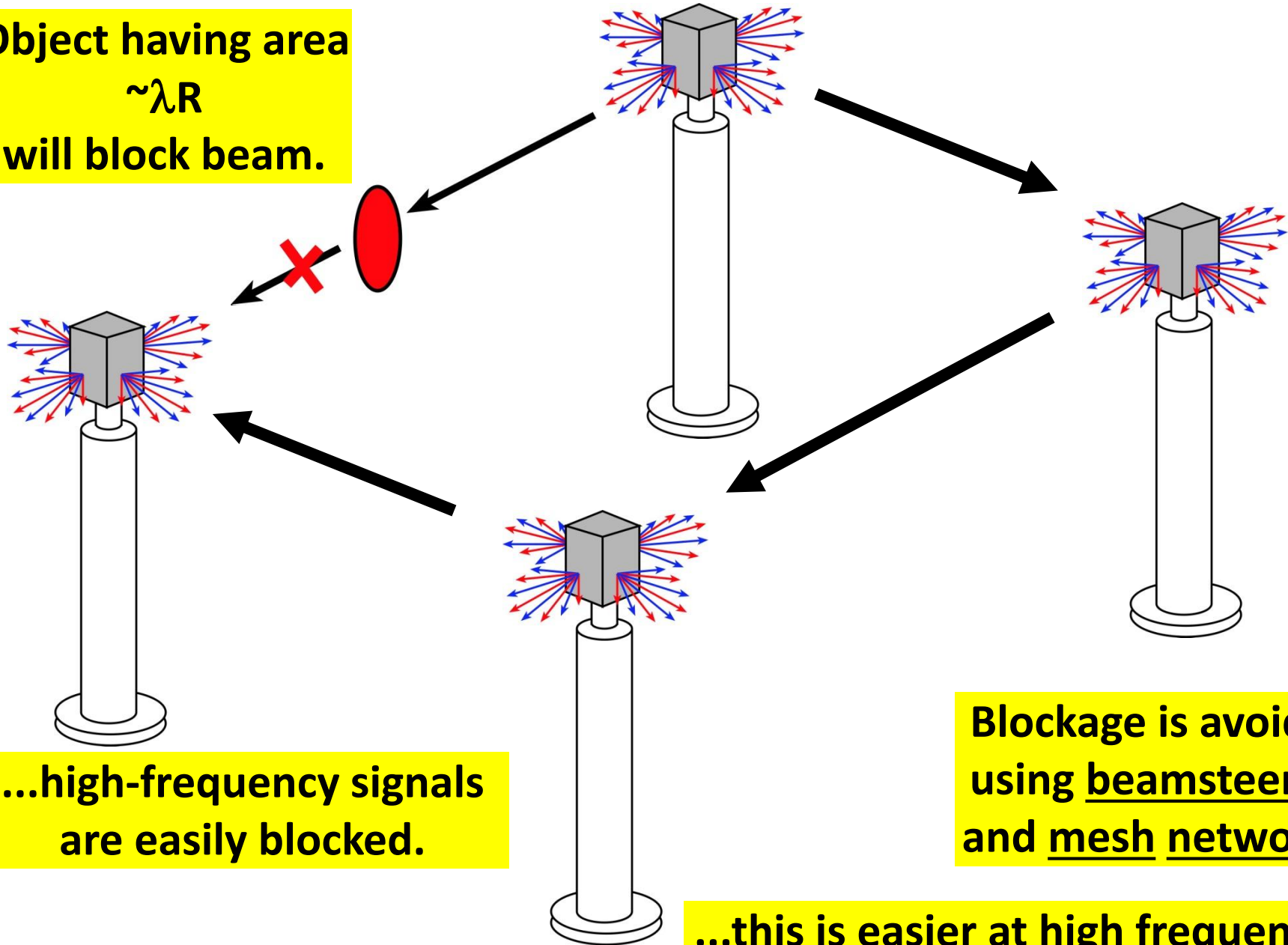


Hardware: multi-beam phased array ICs



100-1000 GHz Wireless Needs Mesh Networks

Object having area
 $\sim \lambda R$
will block beam.



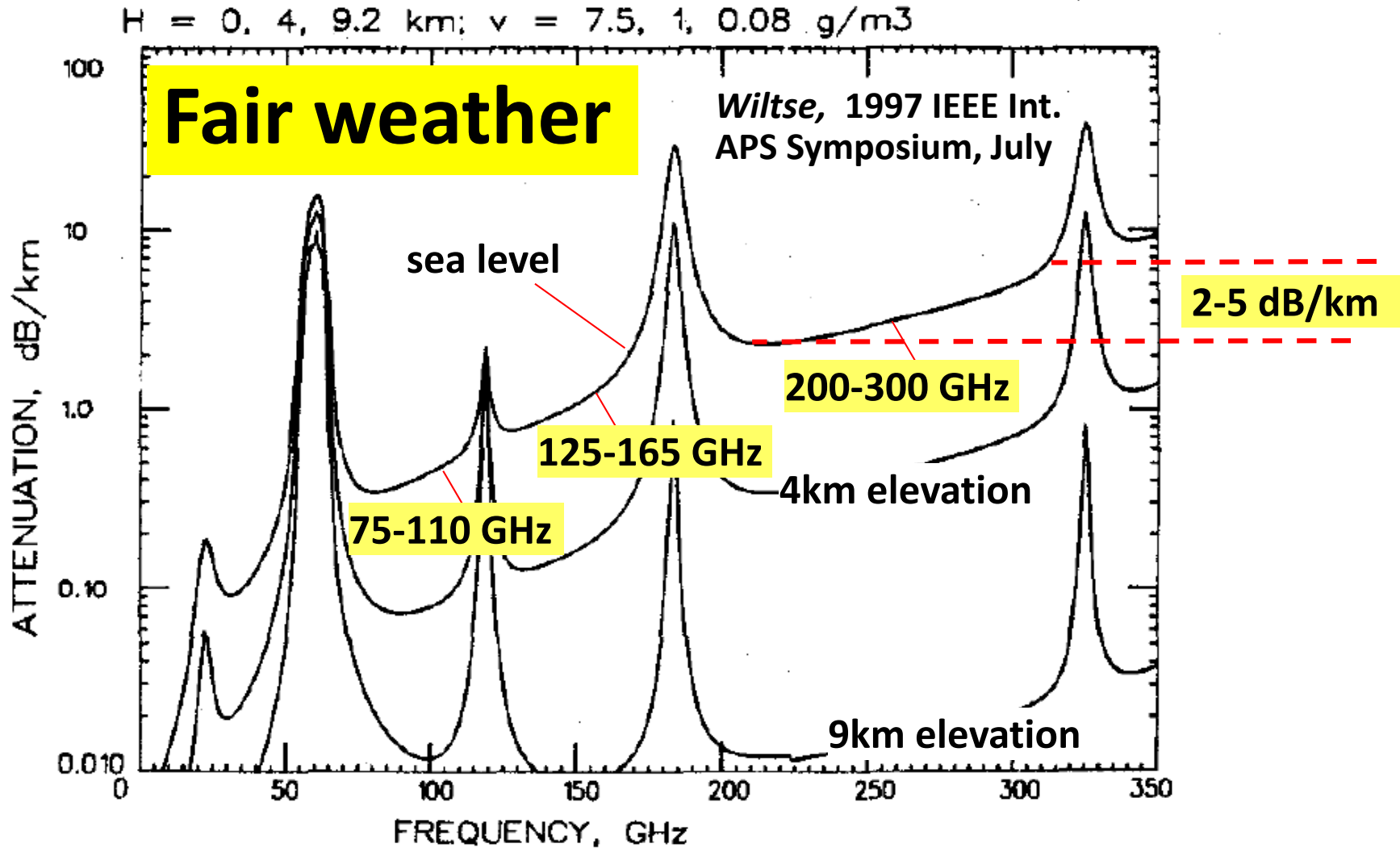
...high-frequency signals
are easily blocked.

Blockage is avoided
using beamsteering
and mesh networks.

...this is easier at high frequencies. 3

mm-wave propagation

Fair-Weather Propagation



Foul Weather Propagation

35°C, 95% Humidity

loss (dB/km) \sim (frequency/60GHz)²

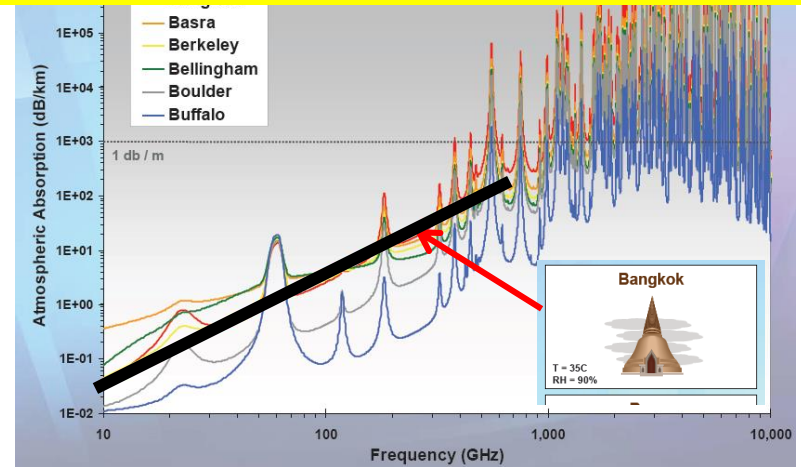
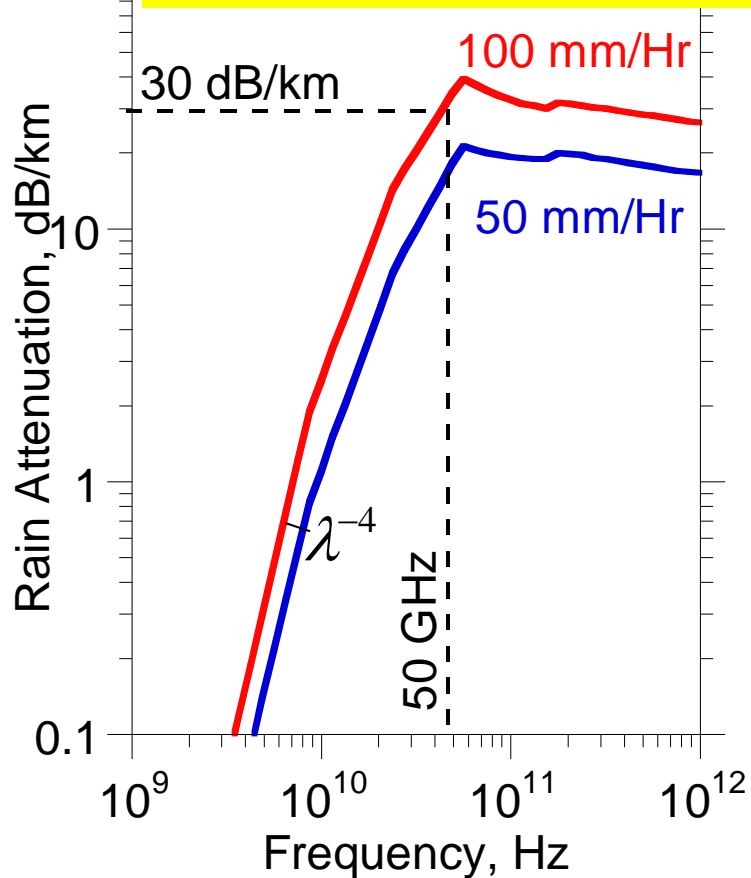
11 dB/km@200 GHz, 5.5dB/km@140GHz

Rain:

10⁻³: 25mm/hr, 11dB/km

10⁻⁴: 50-85mm/hr, 19dB/km

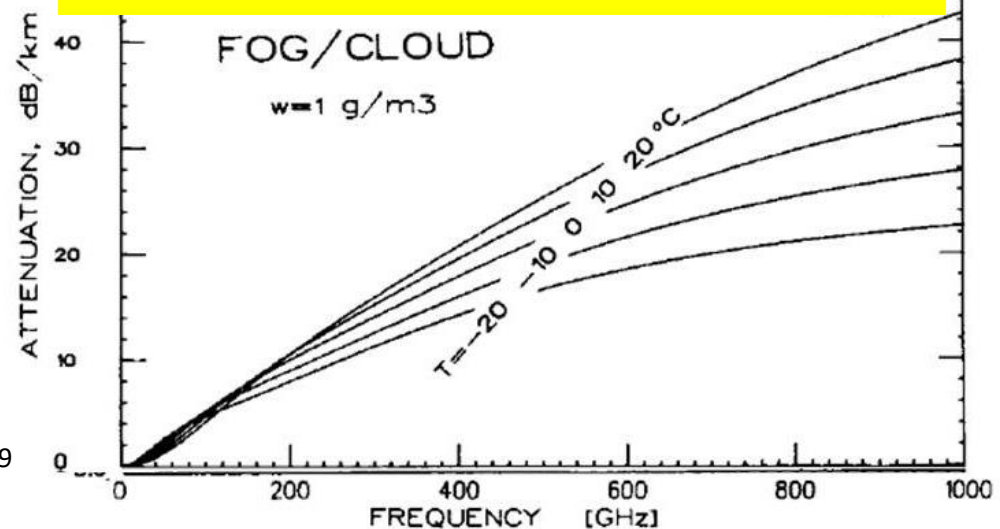
10⁻⁵: 100+mm/hr: 30dB/km



Rosker; Wallace, 2007 IEEE IMS

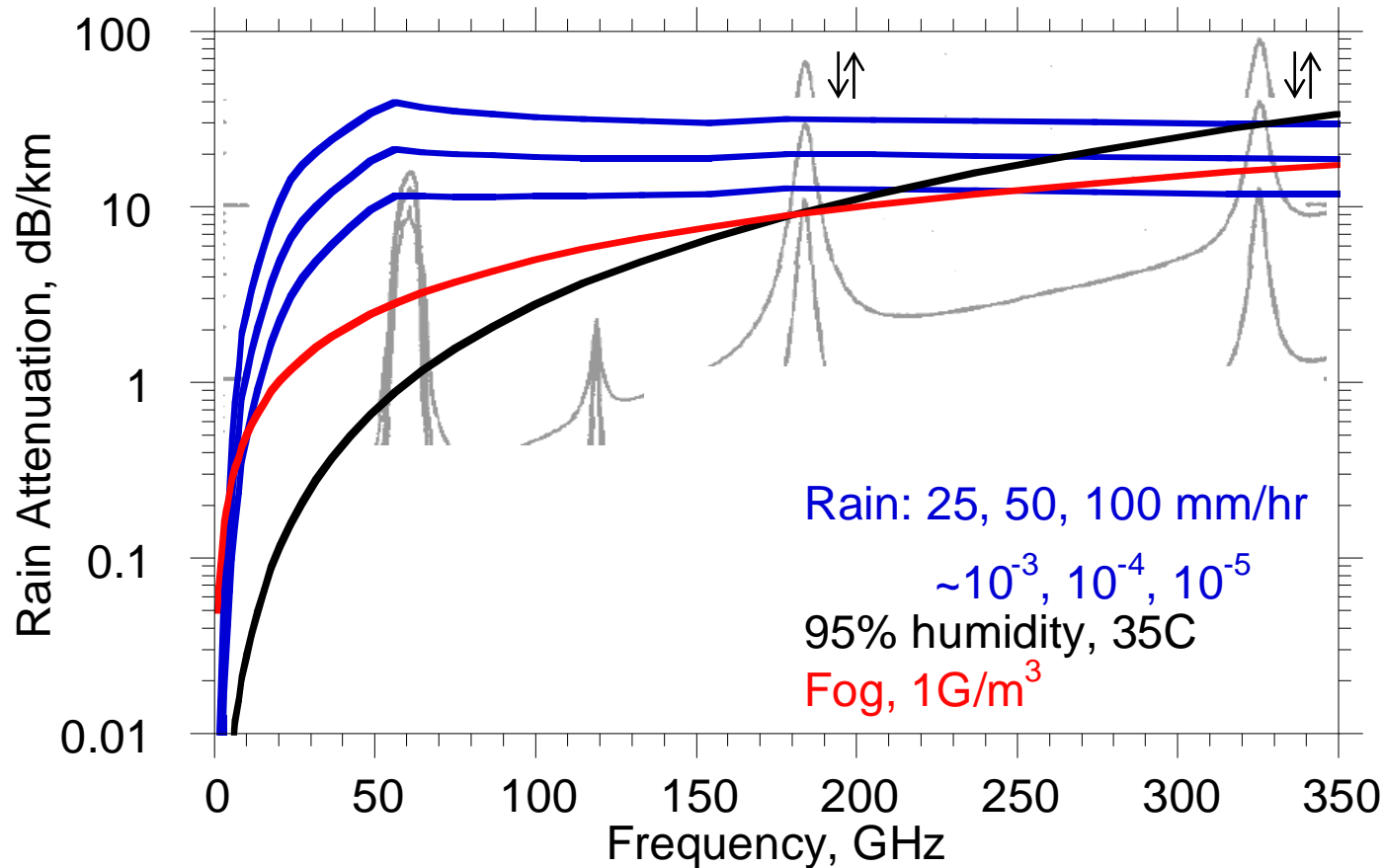
Extreme Fog (1g/m³)

\sim (25 dB/km)x(frequency/500 GHz)



Olsen, Rogers, Hodge, IEEE Trans Antennas & Propagation Mar 1978
 Liebe, Manabe, Hufford, IEEE Trans Antennas and Propagation, Dec. 1989
 Liebe, IEEE Trans Ant and Pro, Vol 31, No. 1, Jan 1983
 Karasawa, Maekawa, IEEE Proc, Vol 85, #6, June 1997

Atmospheric Attenuation: Implications



Worst-case attenuation roughly constant over 50-250 GHz.

10⁻⁵ outage rate: equal losses over 50-300 GHz

10⁻³ outage rate: equal losses over 50-200 GHz

target should be 50-250 GHz links.

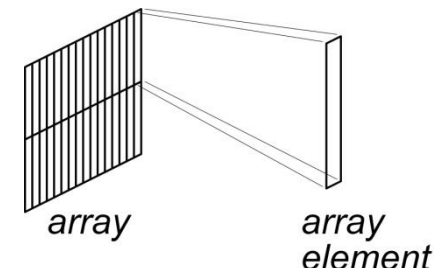
Exclusive use of VLSI Si processes forces use of 50-180GHz

detailed link analysis

Example Link budgets (60 GHz)

The spreadsheet calculates power levels for a point-to-point signal microwave radio link along the surface. To calculate RANGE, vary the range until the transmit power (cell F4) is at the appropriate level

B: Bit rate	1.00E+10	1/sec	4QAM required radiated power	-1.9	dBm	6.426E-04	W
carrier frequency	6.00E+10	Hz	output power per element	-12.0	dBm	6.37E-05	W
λ: wavelength	5.00E-03	m	PA backoff (Ppeak vs Psat)	3.0	dB		
Required SNR (measured as Eb/No)	6.3	dB	PA saturated output power	-9.0	dBm	1.27E-04	W
Receiver bandwidth	2.16E+09	Hz	EIRP	29.7	dBm		
SNR (measured as kT/FB, B from above cell)	13.0	dB	dB EIRP below FCC limits	10.3	dB		
F: receiver noise figure	4.5	dB	Transmitter				
R: transmission range	50.0	m	A_effective	2.89E-03	meters^2	115.49	Wavelengths^2
atmospheric loss	2.653E-02	dB/m	Vertical beam angle, FWHM	2.5	deg	0.0436	radians
Dant, trans transmit antenna directivity	1.45E+03	none	Horizontal beam angle, FWHM	11.3	deg	0.1972	radians
Dant, rcvr receive antenna directivity	1.45E+03	none	array rows and columns	2	# rows	8	# columns
α: bandwidth factor (0.5<α<1)	0.80		total # array elements	16			
radiated channel bandwidth required	8000.0	MHz	vertical angle scanned, total	5.0	deg		
			horizontal angle scanned, total	90.4	deg		
			array height	22.9	wavelengths		
			array width	5.1	wavelengths		
			array height	1.15E-01	meters	4.51	inches
			array width	2.54E-02	meters	1.00	inches
kT	-173.83	dBm (1Hz)	Antenna directivity, dB	31.62	dB		
packaging loss (receiver)	2	dB	Receiver				
packaging loss (transmitter)	2	dB	A_effective	2.89E-03	meters^2	115.49	Wavelengths^2
end-of-life hardware degradation	3	dB	Vertical beam angle, FWHM	2.5	deg	0.0436	radians
hardware design margin	3	dB	Horizontal beam angle, FWHM	11.3	deg	0.1972	radians
beam aiming loss (edge of beam)	3	dB	array rows and columns	2	# rows	8	# columns
systems operating margin	6	dB	vertical angle scanned, total	5	deg		
Prec. received power at 1E-9 BER	-46.00	dBm	horizontal angle scanned, total	90.4	deg		
geometric path loss	1.33E-04		array height	2.3E+01	wavelengths		
geometric path loss, dB	-38.75	dB	array width	5.1E+00	wavelengths		
path obstruction loss (foliage, glass)	4.00	dB	array height	1.15E-01	meters	4.51	inches
atmospheric loss, dB	1.3265581	dB	array width	2.54E-02	meters	1.00	inches
atmospheric loss	26.53	dB/km	Antenna directivity, dB	31.62	dB		



array:
16 elements (2x8)
4.5 x 1.0 inches
11.5 x 2.54 cm

$$P_{received(4QPSK)} = Q^2 \cdot kTfB \quad \text{where } Q = \text{SNR}$$

$$P_{received} / P_{trans} = (D_t D_r / 16\pi^2) (\lambda / R)^2$$

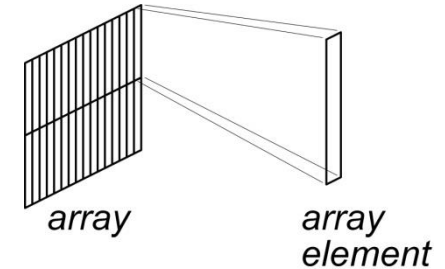
$$D = 4\pi A_{eff} / \lambda^2 \cong \frac{4\pi}{\theta_{FWHM}^{\text{radians}} \phi_{FWHM}^{\text{radians}}} \cong \frac{41,000}{\theta_{FWHM}^{\circ} \phi_{FWHM}^{\circ}}$$

Note various margins allocated.
Rain losses calculated from rain rate.

Example Link budgets (140 GHz)

This spreadsheet calculates power levels for 4QPSK point-point digital microwave radio links along the surface
To calculate RANGE, vary the range until the transmit power (cell F4) is at the appropriate level

B: Bit rate	1.00E+10	1/sec	4QAM required radiated power	6.1	dBm	4.087E-03	W
carrier frequency	1.40E+11	Hz	output power per element	-3.9	dBm	4.05E-04	W
λ : wavelength	2.14E-03	m	PA backoff (Ppeak vs Psat)	3.0	dB		
Required SNR (measured as Eb/No)	6.3	dB	PA saturated output power	-0.9	dBm	8.08E-04	W
Receiver bandwidth	5.00E+09	Hz	EIRP	37.7	dBm		
SNR (measured as kTFB, B from above cell)	9.3	dB	dB EIRP below FCC limits	2.3	dB		
F: receiver noise figure	6	dB	Transmitter				
R: transmission range	50.0	m	A_effective	5.30E-04	meters^2	115.49	Wavelengths^2
atmospheric loss	1.003E-02	dB/m	Vertical beam angle, FWHM	2.5	deg	0.0436	radians
Dant, trans transmit antenna directivity	1.45E+03	none	Horizontal beam angle, FWHM	11.3	deg	0.1972	radians
Dant, rcvr receive antenna directivity	1.45E+03	none	array rows and columns	2	# rows	8	# columns
α : bandwidth factor (0.5< α <1)	0.80		total # array elements	16			
radiated channel bandwidth required	8000.0	MHz	vertical angle scanned, total	5.0	deg		
			horizontal angle scanned, total	90.4	deg		
			array height	22.9	wavelengths		
			array width	5.1	wavelengths		
			array height	4.91E-02	meters	1.93	inches
			array width	1.09E-02	meters	0.43	inches
kT	-173.83	dBm (1Hz)	Antenna directivity, dB	31.62	dB		
packaging loss (receiver)	2	dB	Receiver				
packaging loss (transmitter)	2	dB	A_effective	5.30E-04	meters^2	115.49	Wavelengths^2
end-of-life hardware degradation	3	dB	Vertical beam angle, FWHM	2.5	deg	0.0436	radians
hardware design margin	3	dB	Horizontal beam angle, FWHM	11.3	deg	0.1972	radians
beam aiming loss (edge of beam)	3	dB	array rows and columns	2	# rows	8	# columns
systems operating margin	6	dB	vertical angle scanned, total	5	deg		
Prec, received power at 1E-9 BER	-44.50	dBm	horizontal angle scanned, total	90.4	deg		
geometric path loss	2.45E-05		array height	2.3E+01	wavelengths		
geometric path loss, dB	-46.11	dB	array width	5.1E+00	wavelengths		
path obstruction loss (foliage, glass)	4.00	dB	array height	4.91E-02	meters	1.93	inches
atmospheric loss, dB	0.5013679	dB	array width	1.09E-02	meters	0.43	inches
atmospheric loss	10.03	dB/km	Antenna directivity, dB	31.62	dB		



array:
16 elements (2x8)
1.9 x 0.43 inches
4.9 x 0.11 cm

$$P_{received(4QPSK)} = Q^2 \cdot kTFB \quad \text{where } Q = \text{SNR}$$

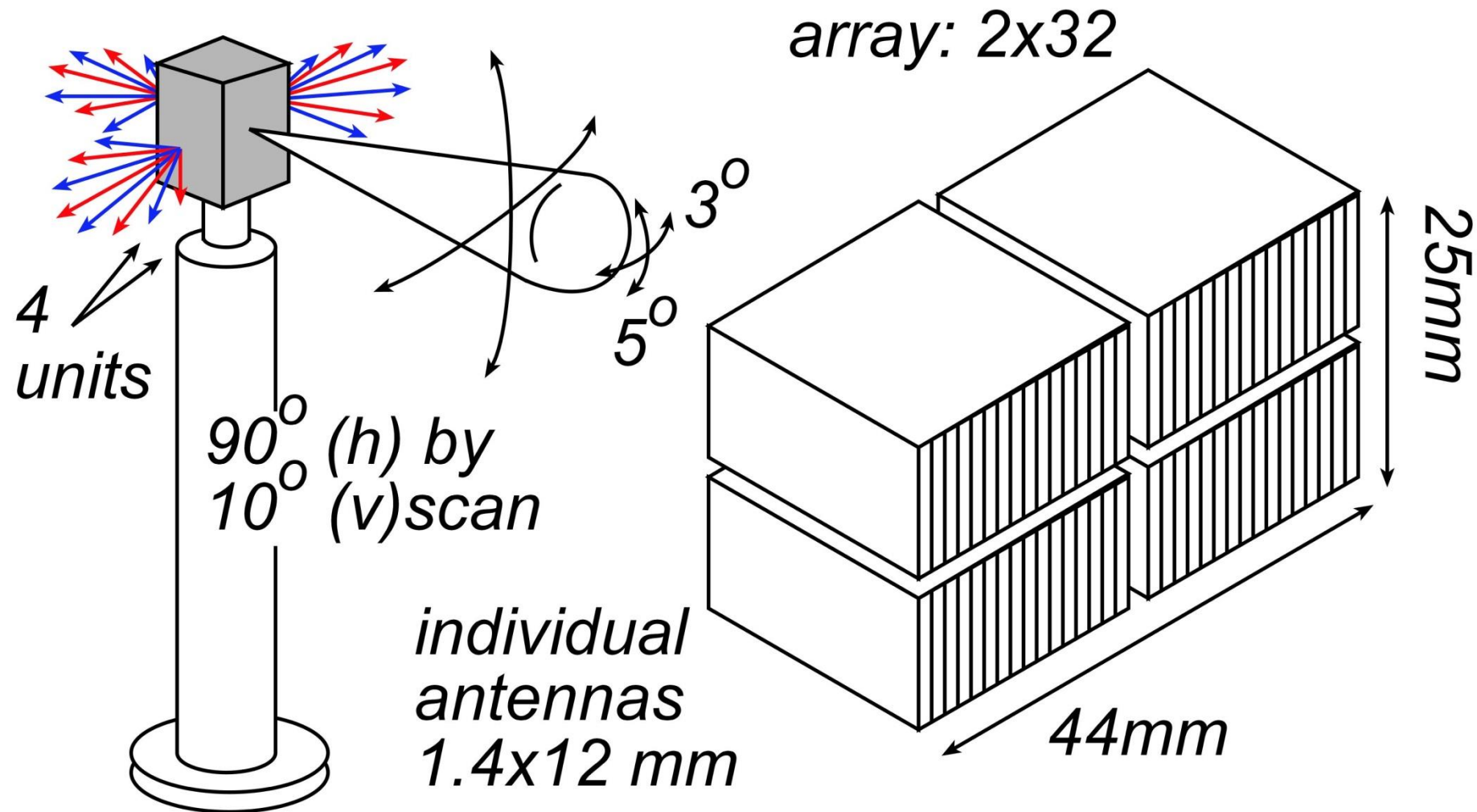
$$P_{received} / P_{trans} = (D_t D_r / 16\pi^2) (\lambda / R)^2$$

$$D = 4\pi A_{eff} / \lambda^2 \cong \frac{4\pi}{\theta_{FWHM}^{\text{radians}} \phi_{FWHM}^{\text{radians}}} \cong \frac{41,000}{\theta_{FWHM}^{\circ} \phi_{FWHM}^{\circ}}$$

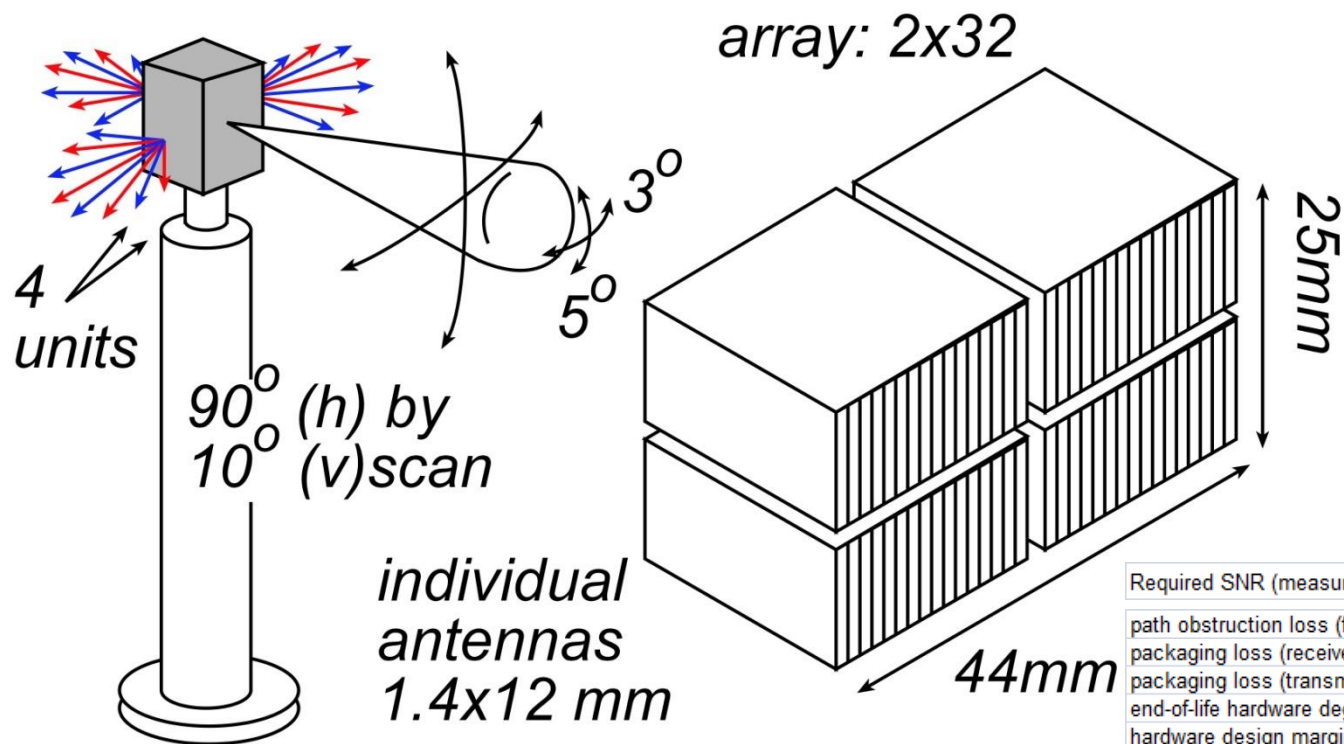
Note various margins allocated.
Rain losses calculated from rain rate.

**hardware:
rough numbers**

140 GHz, 10 Gb/s Adaptive Picocell Backhaul



140 GHz, 10 Gb/s Adaptive Picocell Backhaul



Required SNR (measured as Eb/No)	6.8	dB
path obstruction loss (foliage, glass)	5.00	dB
packaging loss (receiver)	3	dB
packaging loss (transmitter)	3	dB
end-of-life hardware degradation	3	dB
hardware design margin	3	dB
beam aiming loss (edge of beam)	3	dB
systems operating margin	10	dB
PA backoff for OFDM	7.00E+00	dB

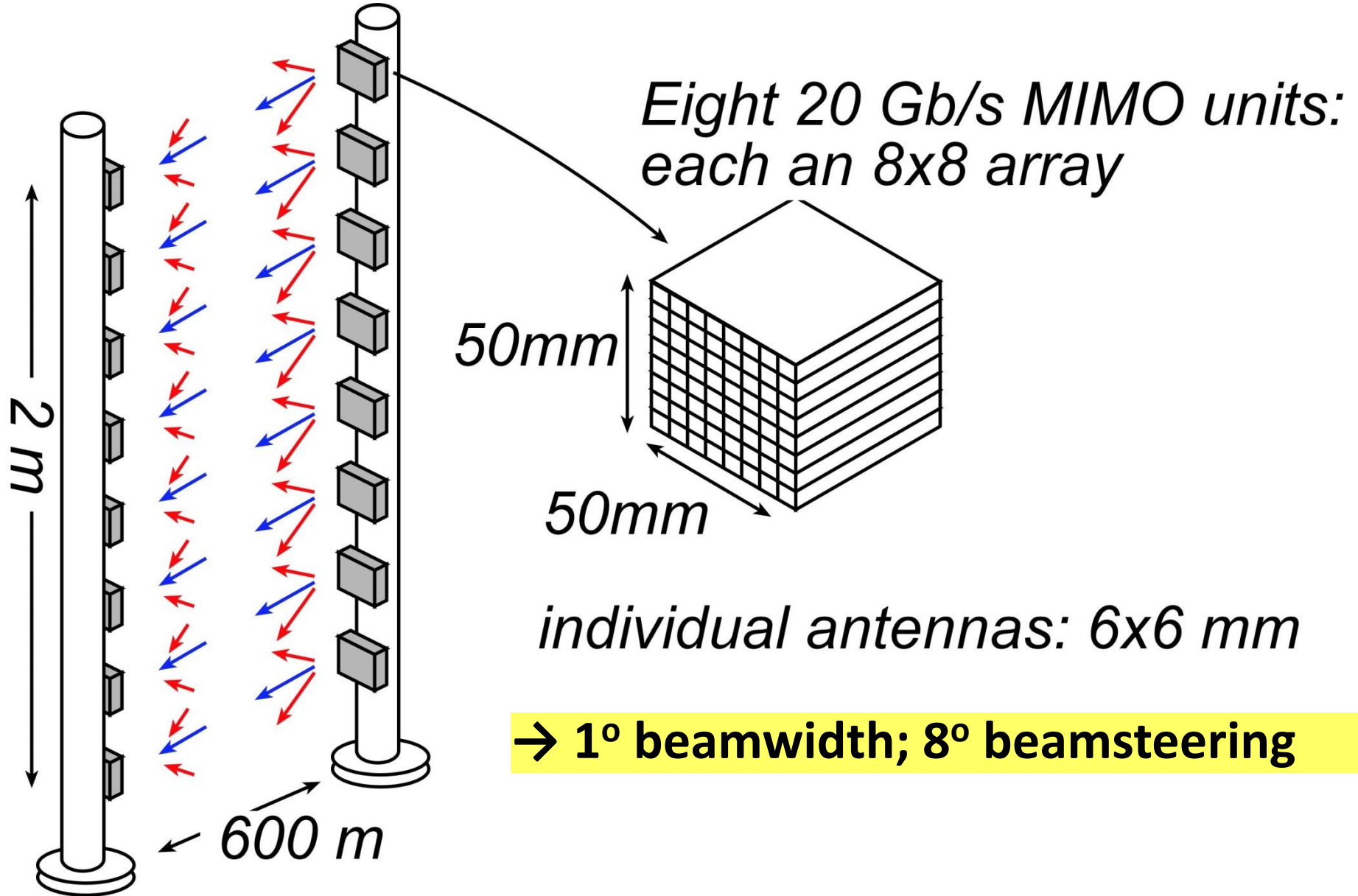
350 meters range in 50mm/hr rain

Realistic packaging loss, operating & design margins

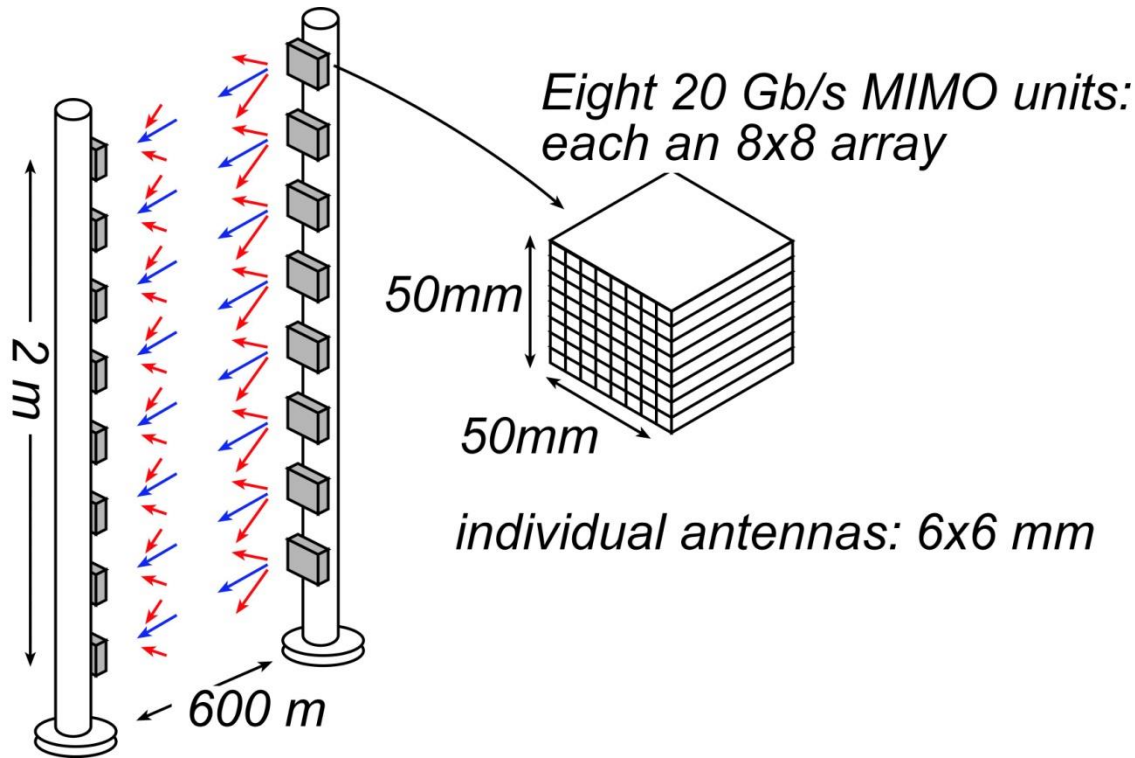
PAs: 24 dBm P_{sat} (per element)

LNAs: 4 dB noise figure

340 GHz, 160 Gb/s MIMO Backhaul Link



340 GHz, 160 Gb/s MIMO Backhaul Link



1° beamwidth; 8° beamsteering

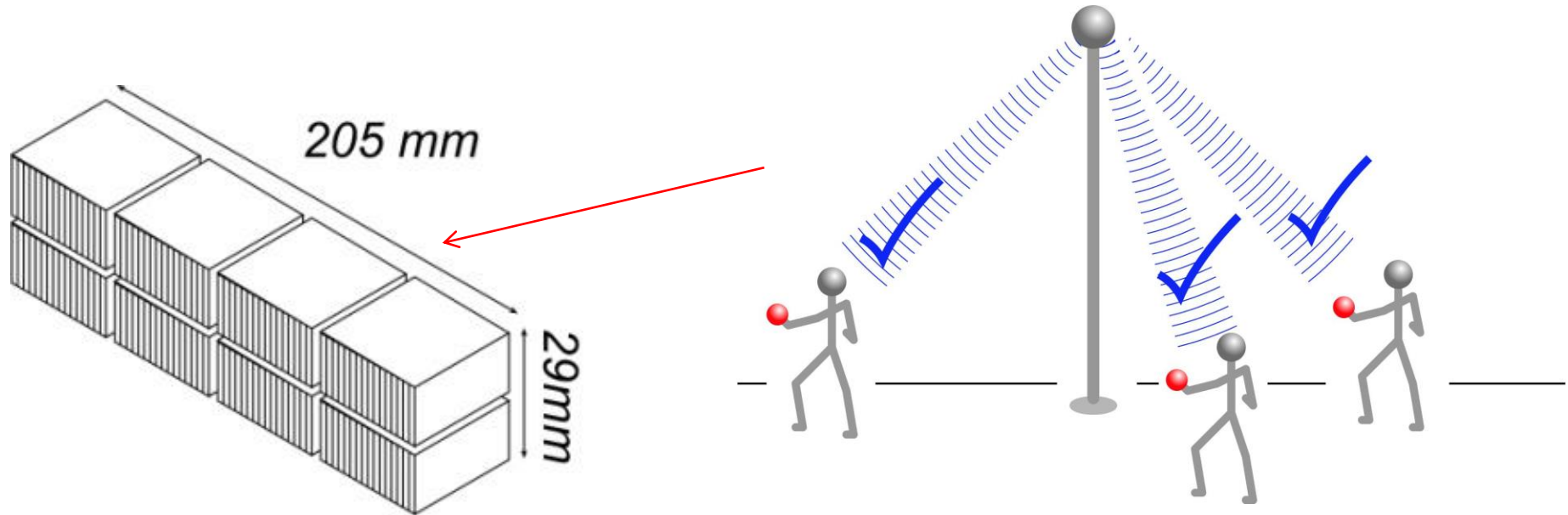
600 meters range in five-9's rain

Realistic packaging loss, operating & design margins

PAs: 21 dBm P_{sat} (per element)

LNAs: 7 dB noise figure

60 GHz, 1 Tb/s Spatially-Multiplexed Base Station



2x64 array on each of four faces.

Each face supports 128 users, 128 beams: 512 total users.

Each beam: 2Gb/s.

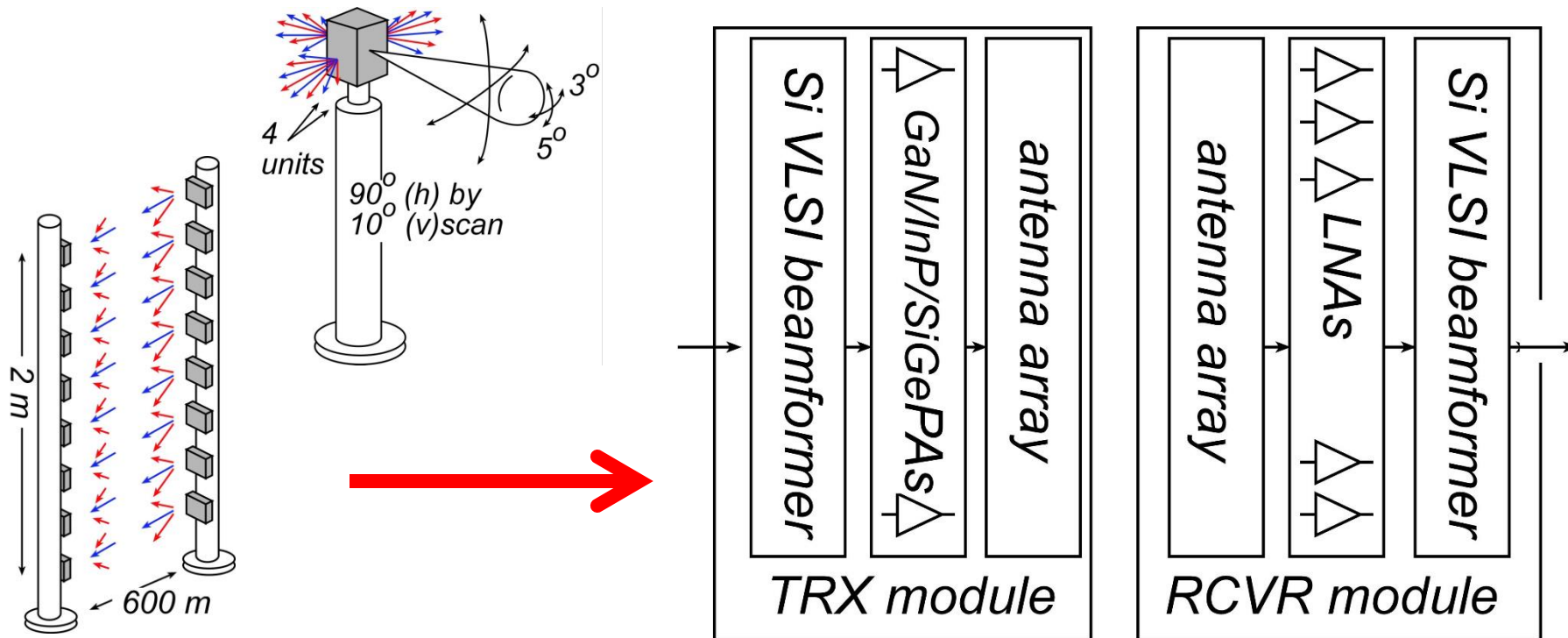
200 meters range in 50 mm/hr rain

Realistic packaging loss, operating & design margins

PAs: 20 dBm P_{out} , 26 dBm P_{sat} (per element)

LNAs: 3 dB noise figure

mm-Wave Wireless Transceiver Architecture



custom PAs, LNAs → power, efficiency, noise
Si CMOS beamformer → integration scale

...similar to today's cell phones.

400 GHz frequency-scanned imaging radar

What your eyes see-- in fog



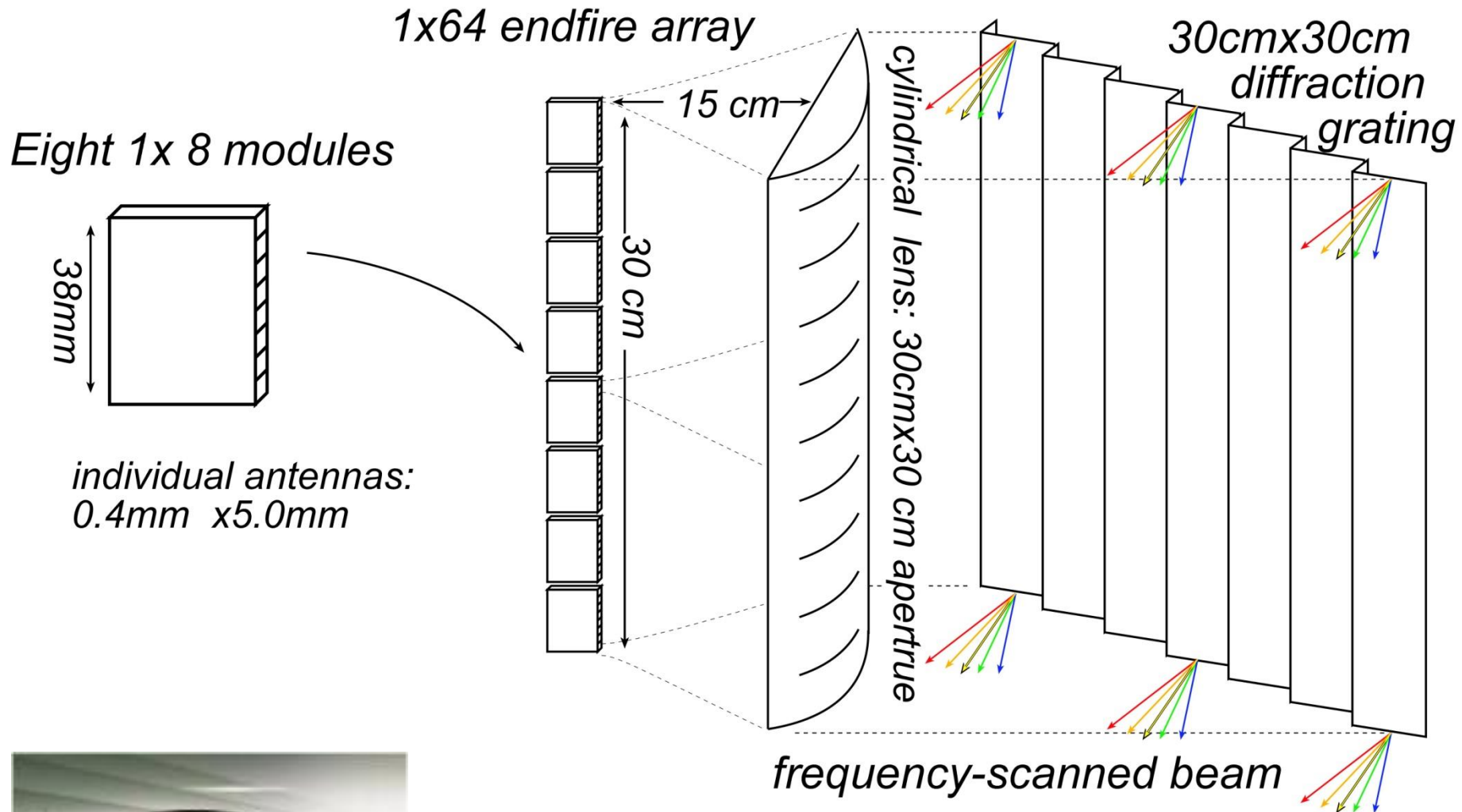
What you see with X-band radar



What you would like to see



400 GHz frequency-scanned imaging car radar



400 GHz frequency-scanned imaging car radar

Range: see a basketball at 300 meters (10 seconds warning) in heavy fog
(10 dB SNR, 28 dB/km, 1 foot diameter target, 65 MPH)

Image refresh rate: 60 Hz

Resolution $64 \times 512 = 32,800$ pixels

Angular resolution: 0.10 degrees

Angular field of view: 9 by 97 degrees

Aperture: 12" by 12"

Component requirements:

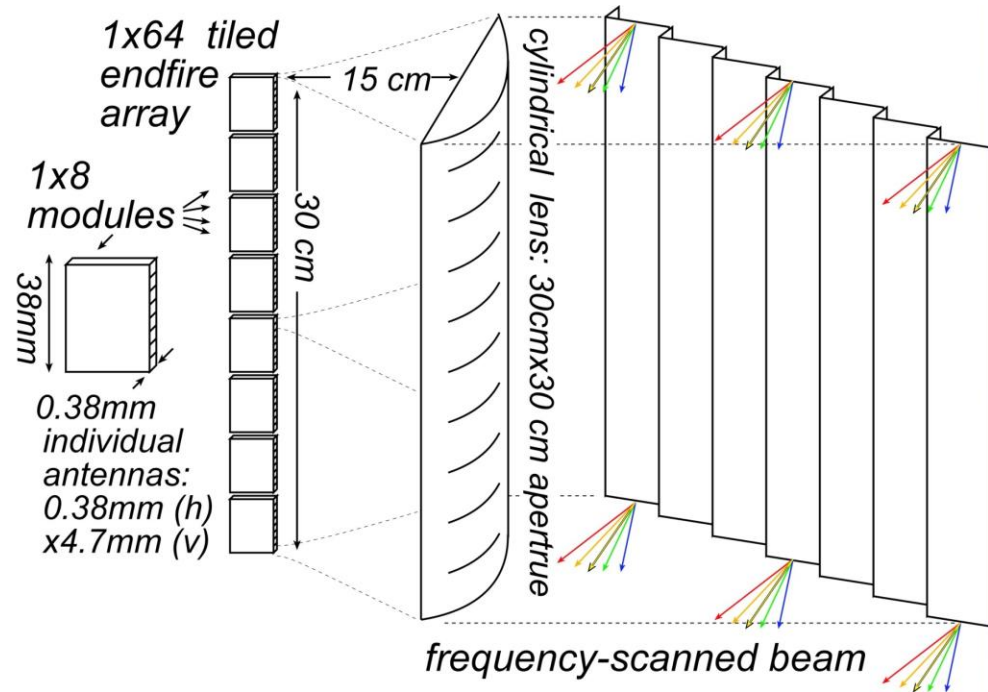
10 mW peak power/element,

3% pulse duty factor

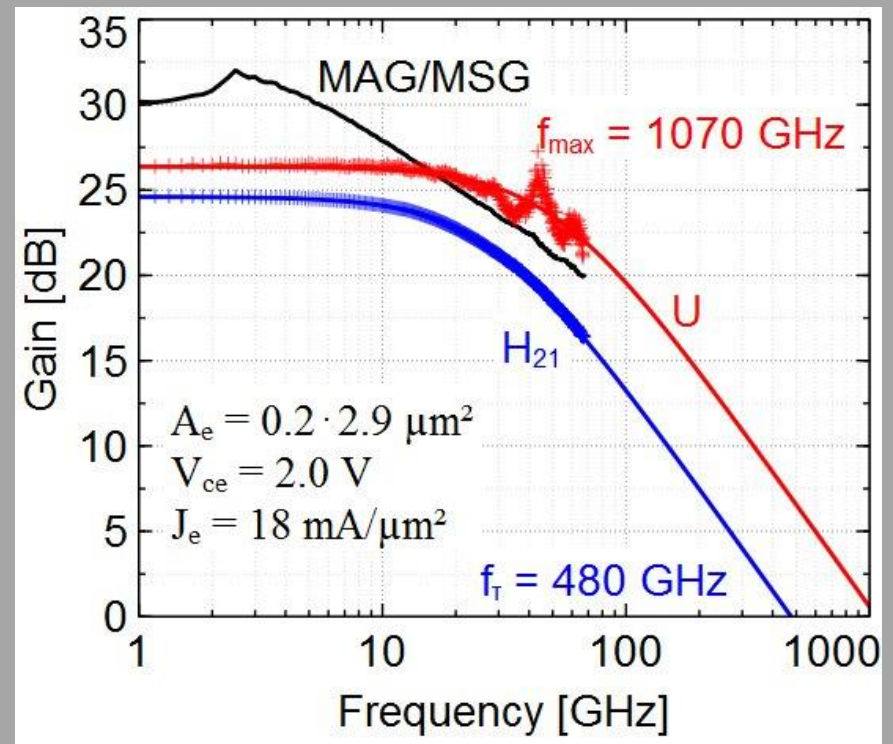
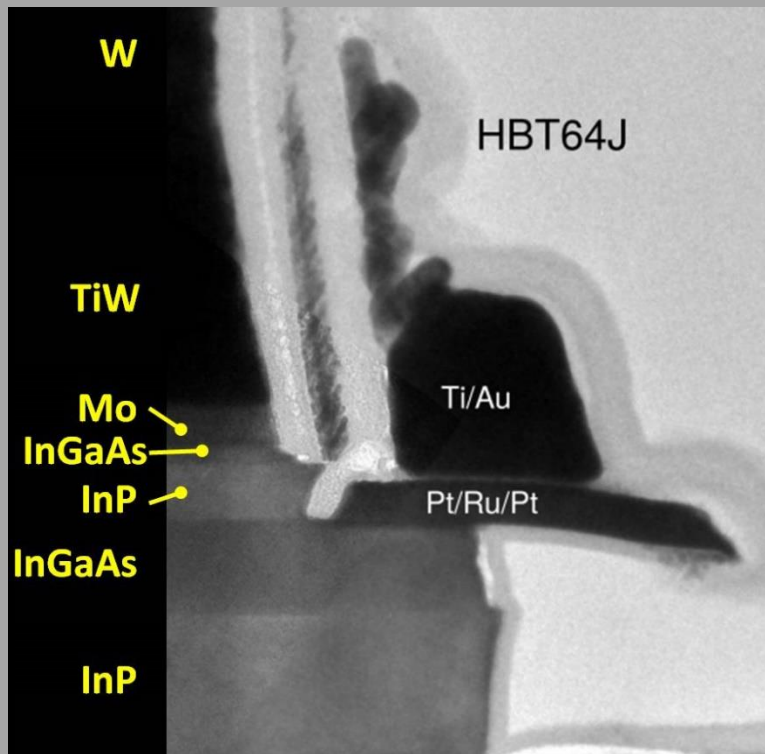
6.5 dB noise figure,

5 dB package losses

5 dB manufacturing/aging margin



Transistors and IC technologies

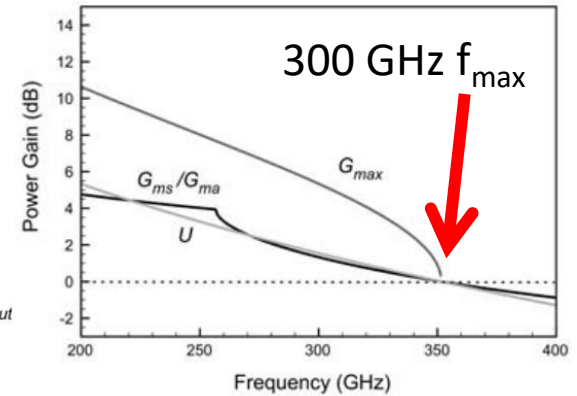
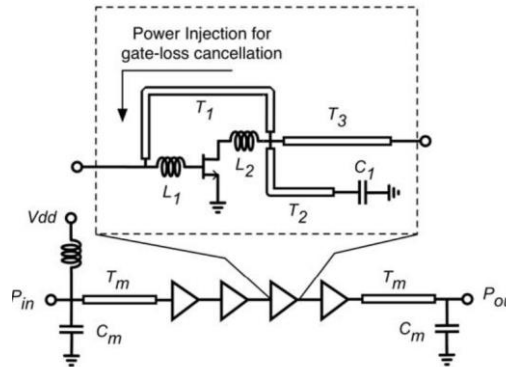
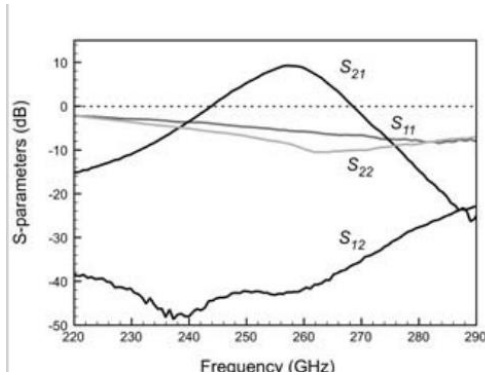


mm-wave CMOS (examples)

260 GHz amplifier:

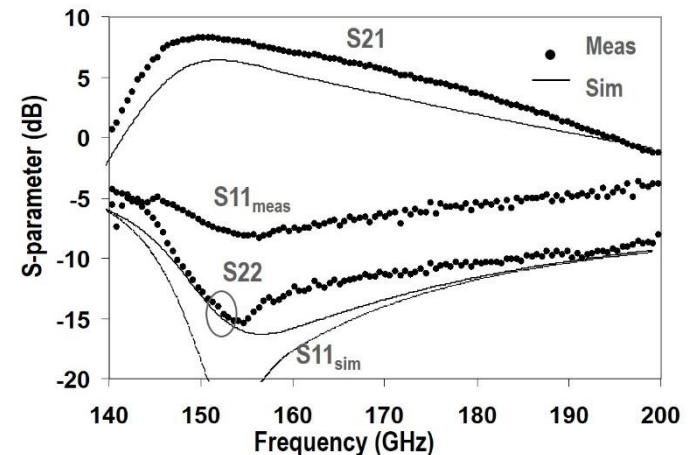
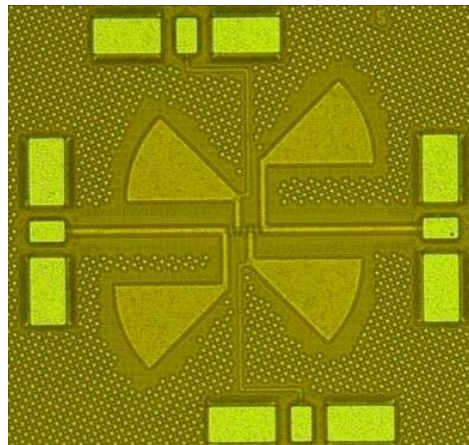
65nm bulk CMOS, Over-neutralized to reach G_{max} , 9.2 dB, 4 stages

Momeni ISSCC, March 2013



150 GHz amplifier: 65 nm bulk CMOS, 8.2 dB, 3 stages (250GHz f_{max})

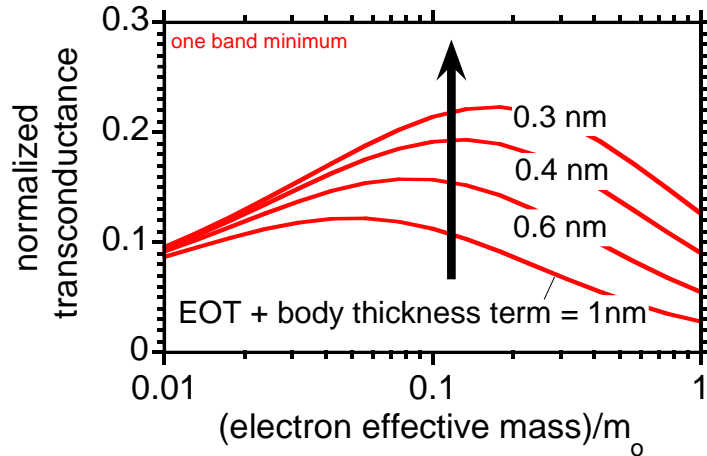
Seo et al. (UCSB), JSSC, December 2009



mm-Wave CMOS won't scale much further

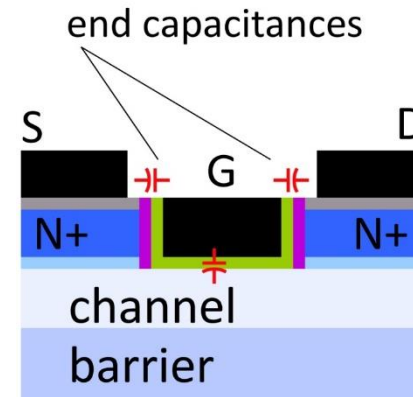
Gate dielectric can't be thinned

→ on-current, g_m can't increase



Shorter gates give no less capacitance

dominated by ends; $\sim 1\text{fF}/\mu\text{m}$ total

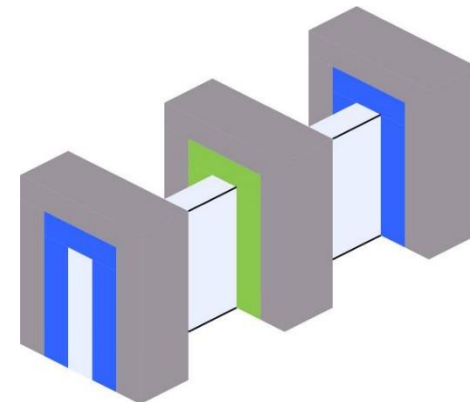


Maximum g_m , minimum $C \rightarrow$ upper limit on f_T
about 350-400 GHz.

Tungsten via resistances reduce the gain

Inac et al, CSICS 2011

Present finFETs have yet larger end capacitances

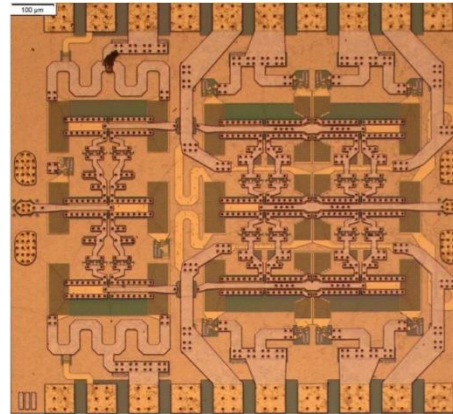


III-V high-power transmitters, low-noise receivers

Cell phones & WiFi:
GaAs PAs, LNAs

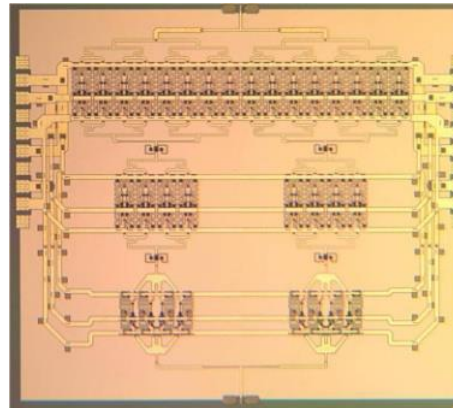


mm-wave links need
high transmit power,
low receiver noise



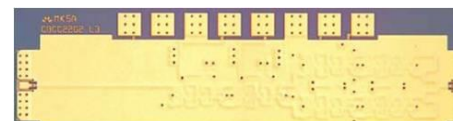
0.47 W @86GHz

H Park, UCSB, IMS 2014



0.18 W @220GHz

T Reed, UCSB, CSICS 2013



1.9mW @585GHz

M Seo, TSC, IMS 2013

InP Bipolar Transistors

Why InP Bipolar Transistors ?

InP better electron transport than Si collectors

higher electron velocity 3.5 vs 1.0×10^7 cm/s
plus wider bandgap \rightarrow higher breakdown field

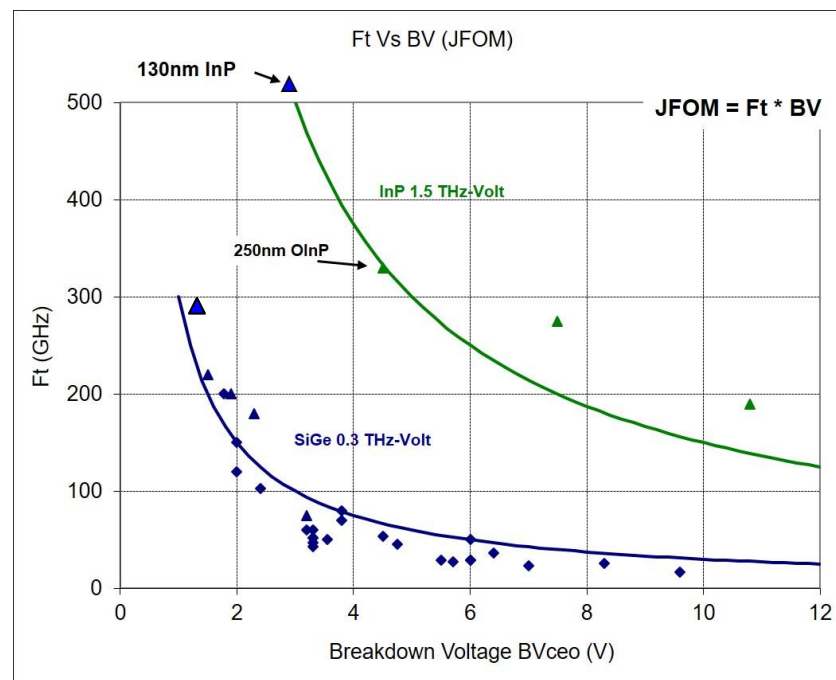
InGaAs base, base-emitter heterojunction:

very low base sheet resistances

Implications:

$\sim 3:1$ higher (f_τ , f_{\max}) at a given scaling node
higher breakdown* at a given (f_τ , f_{\max})

but...InP HBT not a production technology



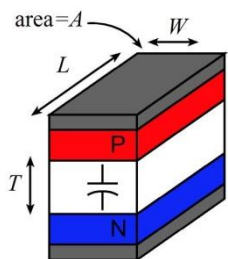
*Breakdown is too complicated to summarize with BV_{CE0} .

$BVCBO$ vs. BV_{CE0} vs. safe operating area ?

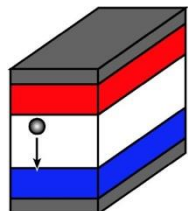
Bottom line: look at V_{ce} used in published IC data for a given IC technology.

Transistor scaling laws: (V,I,R,C,τ) vs. geometry

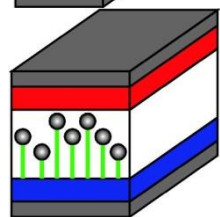
Depletion Layers



$$C = \epsilon \cdot \frac{A}{T}$$

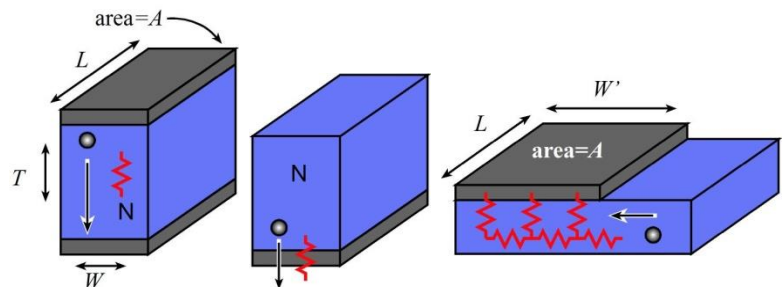


$$\tau = \frac{T}{2v}$$



$$\frac{I_{\max}}{A} = \frac{4\epsilon v_{\text{sat}} (V_{\text{appl}} + \phi)}{T^2}$$

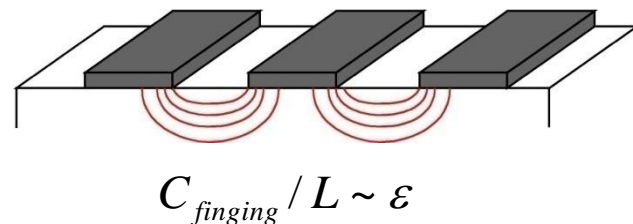
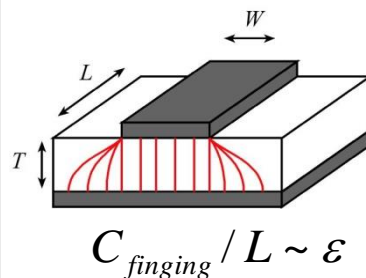
Bulk and Contact Resistances



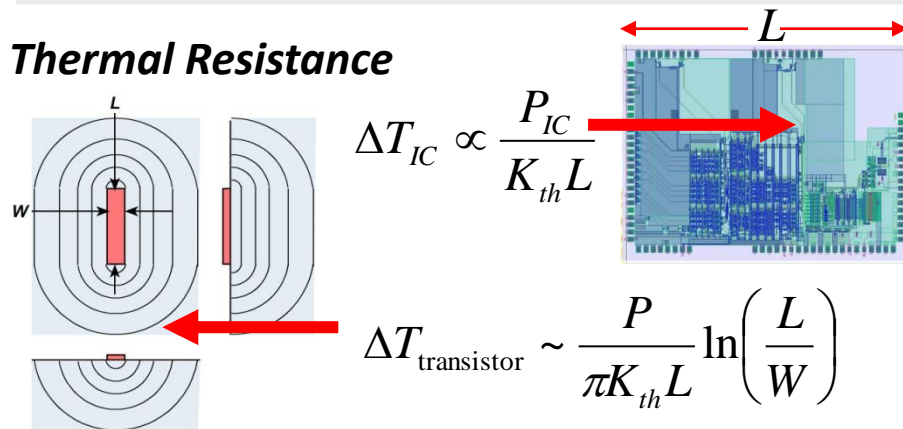
$$R \cong \rho_{\text{contact}} / A \quad \text{contact to rms dominate}$$

Fringing Capacitances

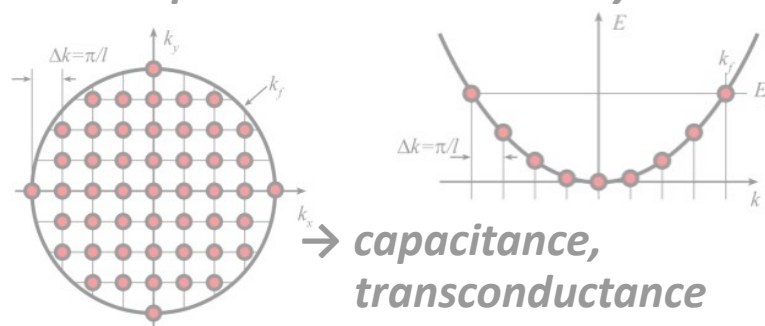
- 1) FET fringing capacitances
- 2) IC interconnect capacitances



Thermal Resistance

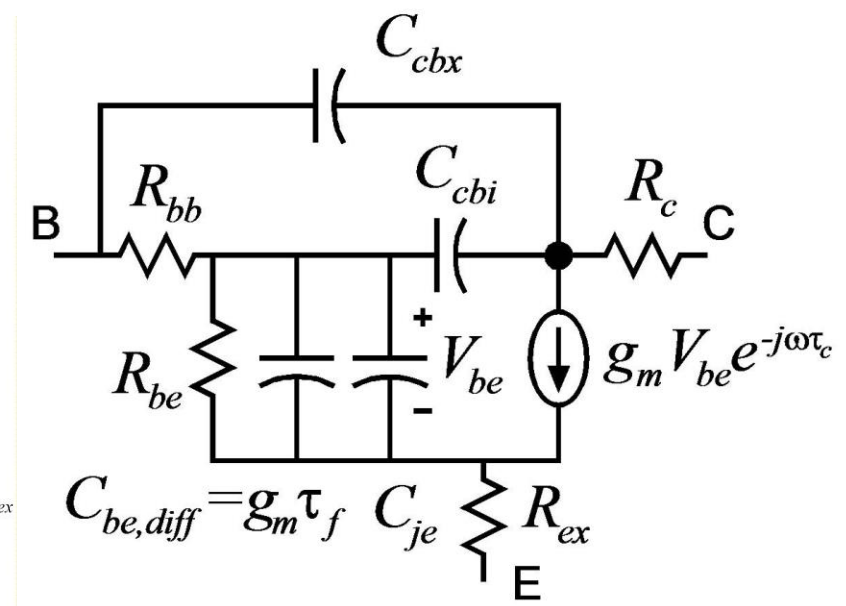
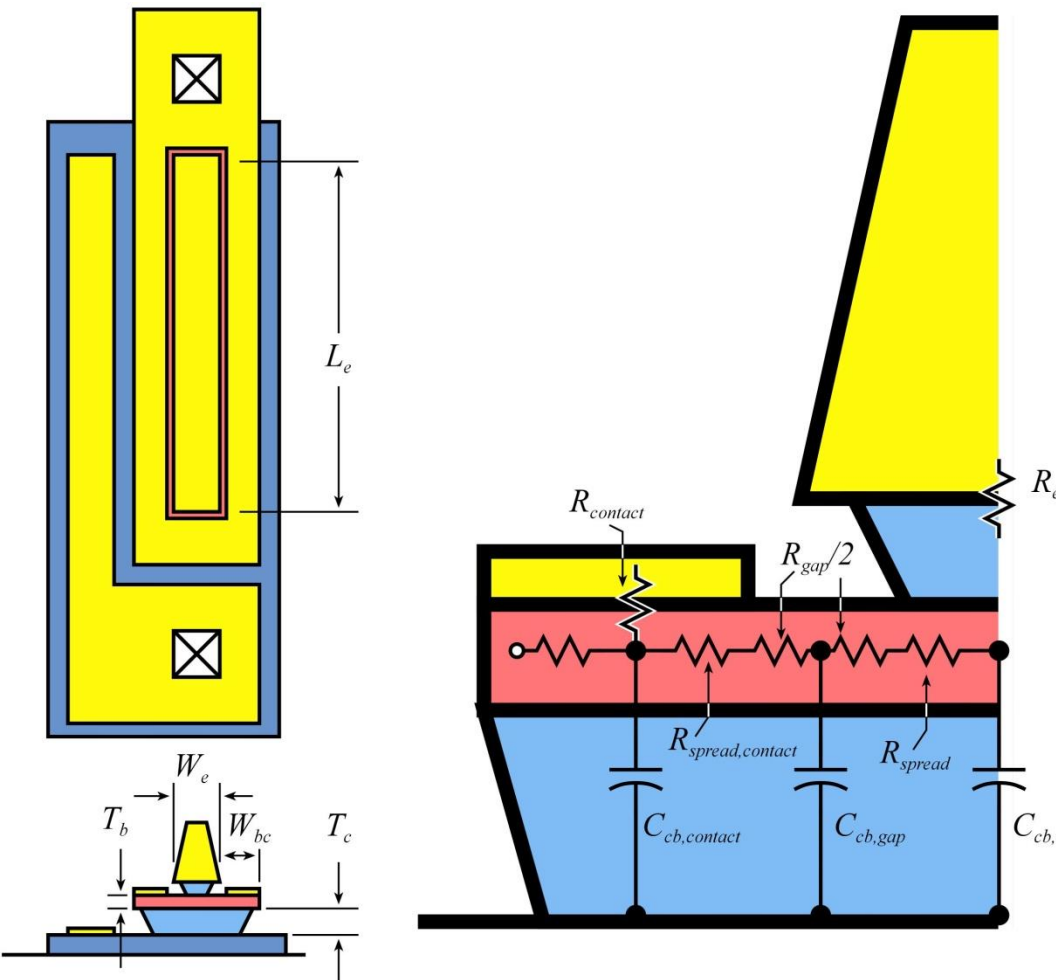


Available quantum states to carry current



→ capacitance,
transconductance
contact resistance

Bipolar Transistor: Structure & Models



$$R_{be} = \beta / g_m$$

$$g_m = qI_E / nkT$$

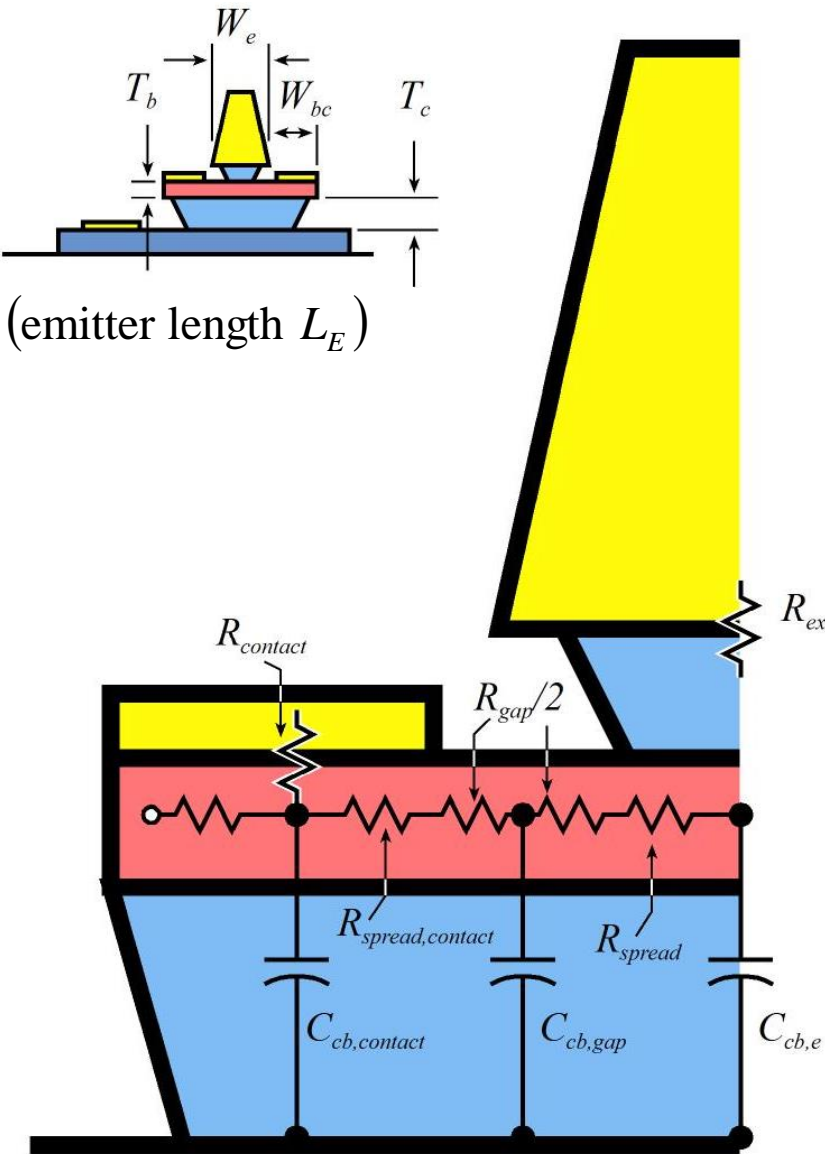
$$C_{be} = C_{je} + g_m (\tau_b + \tau_c)$$

$$\tau_b \approx T_b^2 / 2D_n + T_b / v_{thermal}$$

$$\tau_c \approx T_c / 2v_{sat}$$

$$\frac{1}{2\pi f_\tau} = \tau_{base} + \tau_{collector} + C_{je} \frac{nkT}{qI_E} + C_{bc} \left(\frac{nkT}{qI_E} + R_{ex} + R_{coll} \right)$$

Base-Collector Distributed RC Parasitics



$$R_{ex} = \rho_{contact,emitter} / A_{emitter}$$

$$R_{spread} = \rho_s W_e / 12 L_E$$

$$R_{gap} = \rho_s W_{gap} / 4 L_E$$

$$R_{spread,contact} = \rho_s W_{bc} / 6 L_E$$

$$R_{contact} = \rho_{contact,base} / A_{base_contacts}$$

$$C_{cb,e} = \epsilon A_{emitter} / T_c$$

$$C_{cb,gap} = \epsilon A_{gap} / T_c$$

$$C_{cb,contact} = \epsilon A_{base_contacts} / T_c$$

$R_{bb}C_{cb}$ Time Constant, f_{max} , Simple Hybrid- π model

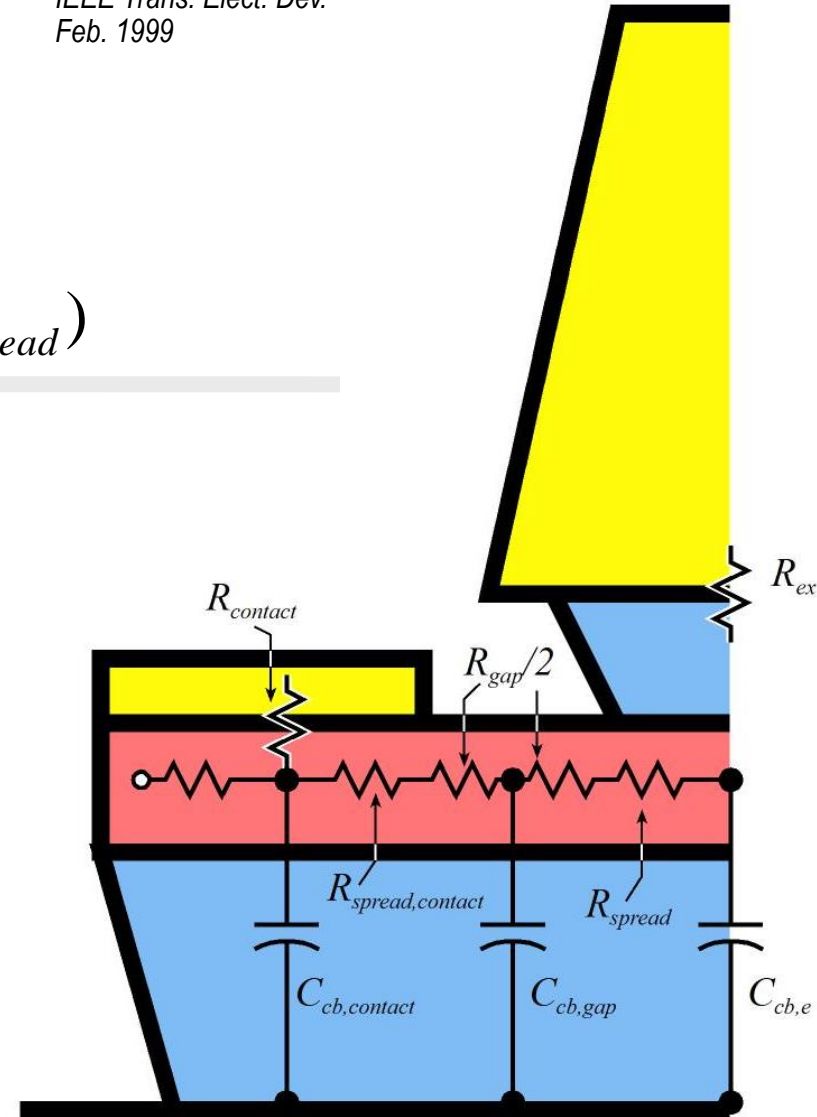
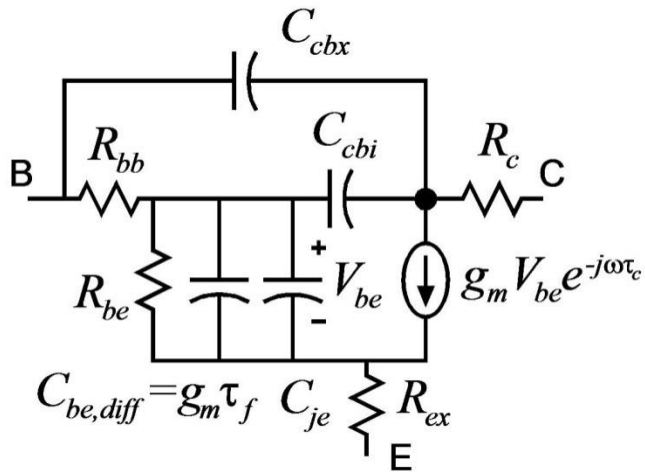
Vaidyanathan & Pulfrey
 IEEE Trans. Elect. Dev.
 Feb. 1999

$$f_{max} \cong \sqrt{f_{\tau} / 8\pi R_{bb} C_{cbi}} \text{ where}$$

$$\tau_{cb} = R_{bb} C_{cbi} = C_{cb,contact} R_{contact}$$

$$+ C_{cb,gap} (R_{contact} + R_{spread,contact} + R_{gap} / 2)$$

$$+ C_{cb,e} (R_{contact} + R_{spread,contact} + R_{gap} + R_{spread})$$

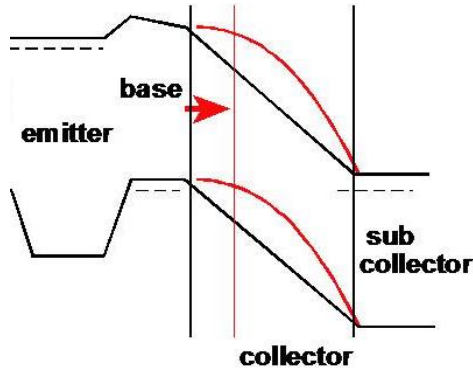


R_{bb} = true total base resistance

$C_{cbi} + C_{cbx}$ = true total C_{cb}

$C_{cbi} : C_{cbx}$ ratio set to fit f_{max} from above

BJT Space-Charge-Limited Current (Kirk effect)

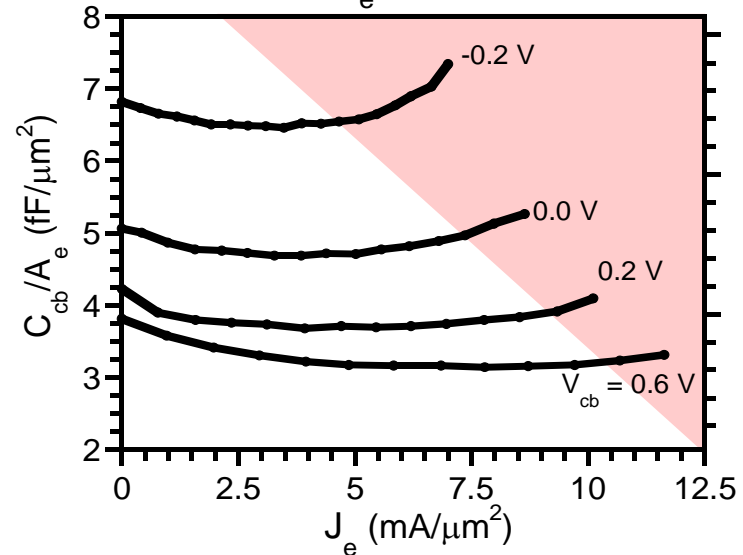
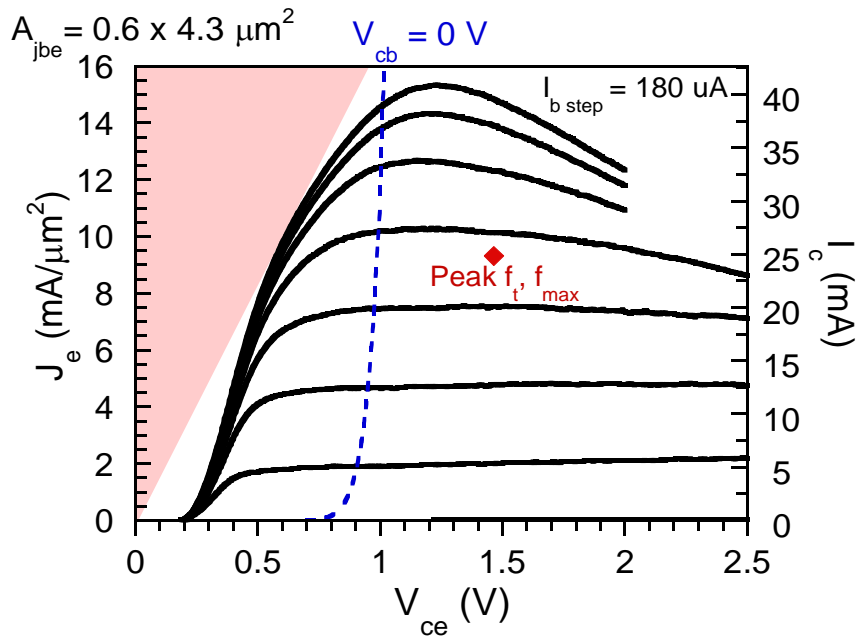
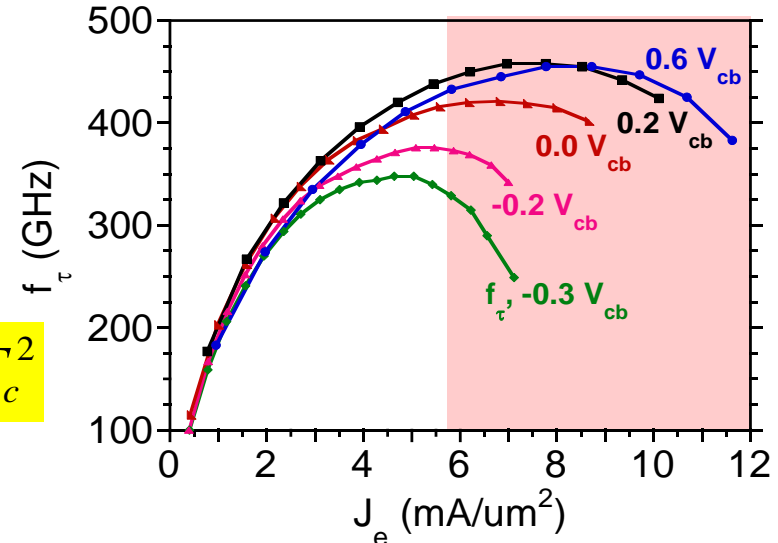


Decreased (f_τ, f_{\max}), increased C_{cb} at high J .

Kirk threshold increases with increased V_{ce} .

$$\partial^2 \phi / \partial x^2 = \rho / \epsilon = (qN_D - J/v) / \epsilon$$

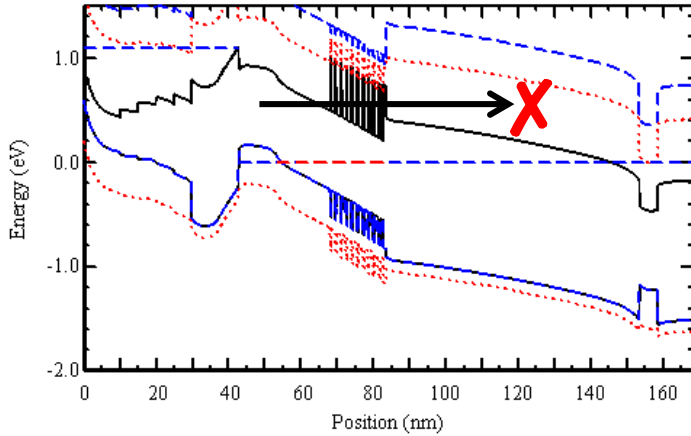
$$\Rightarrow I_{\max} = 2\epsilon v_{\text{eff}} A_E (V_{cb} + V_{cb,\min} + 2\phi) / T_c^2$$



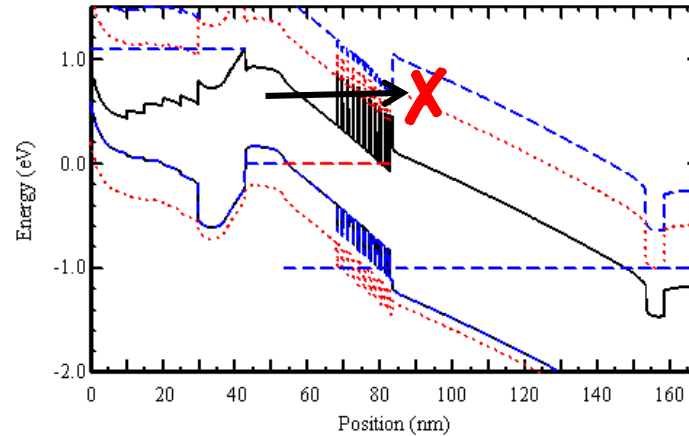
InP: Electron velocity modulation

More collector voltage \rightarrow less distance before scattering \rightarrow more transit time

less collector voltage

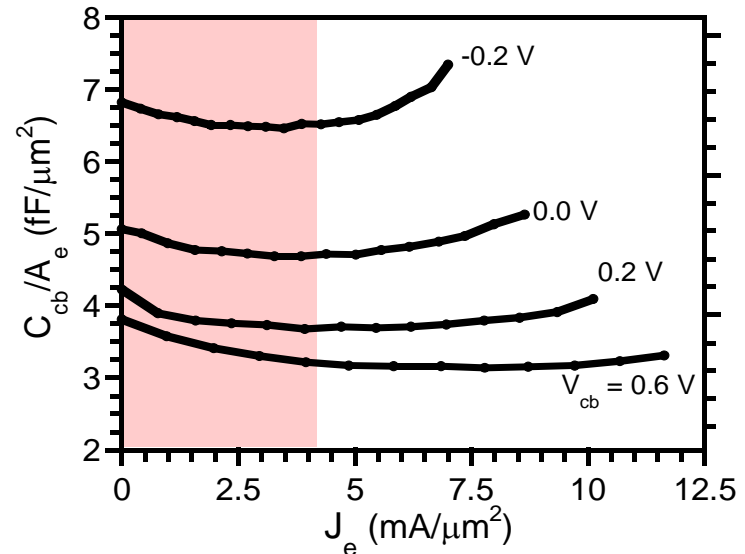
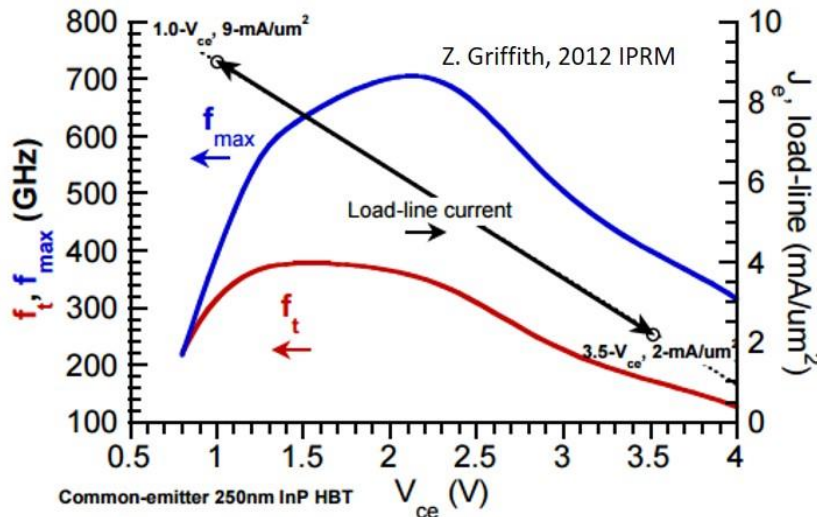


more collector voltage



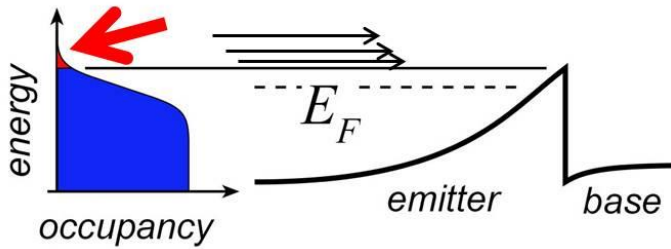
heavy X valley
heavy L valley
light Γ valley

(f_T, f_{max}) decrease with increased V_{ce} . C_{cb} is modulated by I_c .

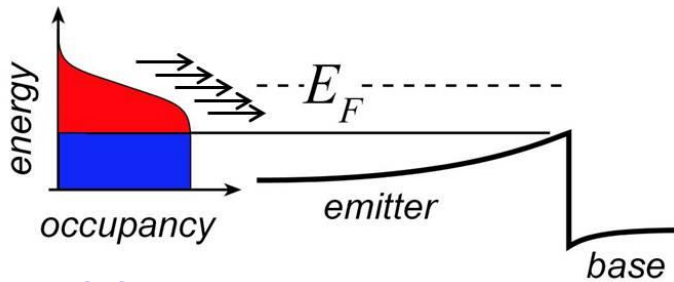


Reduced g_m at extreme current densities

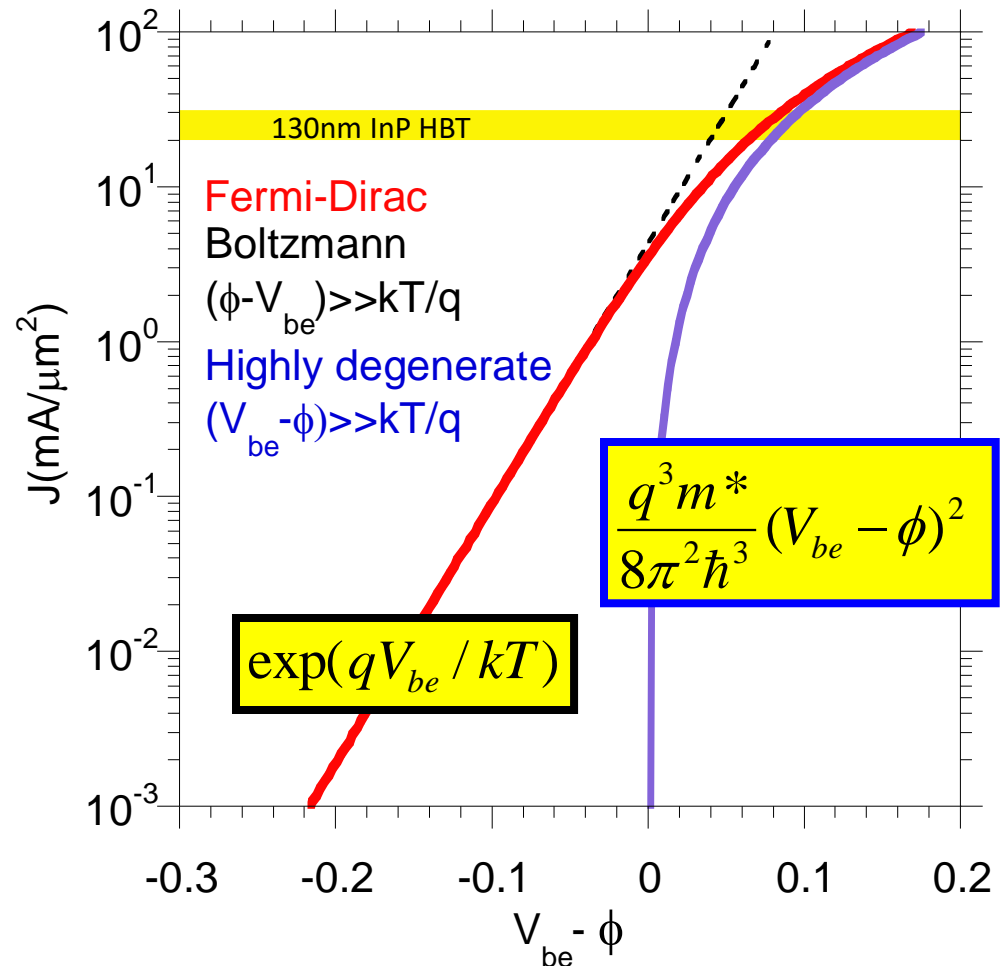
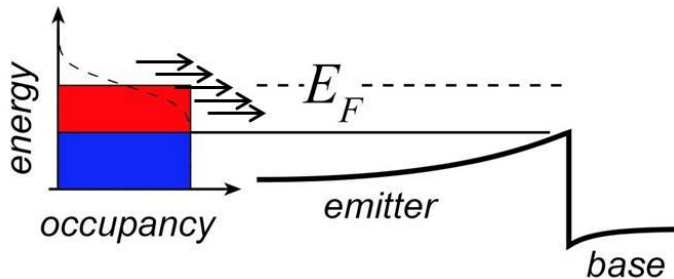
Boltzmann



Fermi-Dirac



Highly Degenerate



High currents \rightarrow transconductance less than $qI/kT \rightarrow$ bandwidth decreases

Problem in InP, not silicon: silicon has larger electron effective mass, more valleys

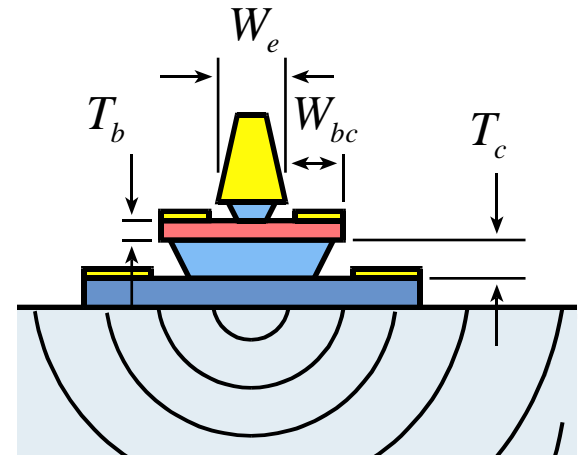
Bipolar Transistor Design

$$\tau_b \approx T_b^2 / 2D_n$$

$$\tau_c = T_c / 2v_{sat}$$

$$C_{cb} = \epsilon A_c / T_c$$

$$I_{c,max} \propto v_{sat} A_e (V_{ce,operating} + V_{ce,punch-through}) / T_c^2$$



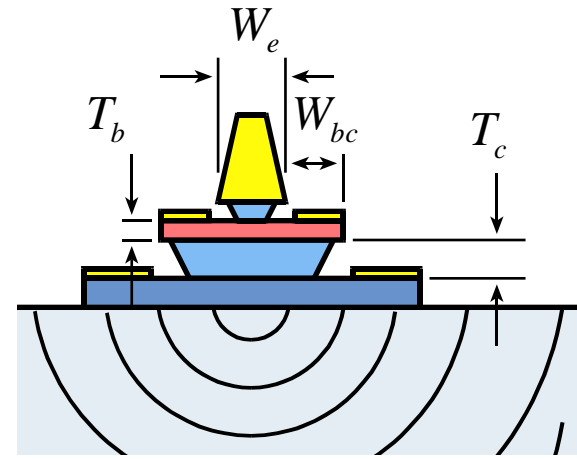
(emitter length L_E)

$$\Delta T \propto \frac{P}{L_E} \left[1 + \ln \left(\frac{L_E}{W_e} \right) \right]$$

$$R_{ex} = \rho_{contact} / A_e$$

$$R_{bb} = \rho_{sheet} \left(\frac{W_e}{12L_e} + \frac{W_{bc}}{6L_e} \right) + \frac{\rho_{contact}}{A_{contacts}}$$

Bipolar Transistor Design: Scaling



(emitter length L_E)

$$\tau_b \approx T_b^2 / 2D_n$$

$$\tau_c = T_c / 2v_{sat}$$

$$C_{cb} = \epsilon A_c / T_c$$

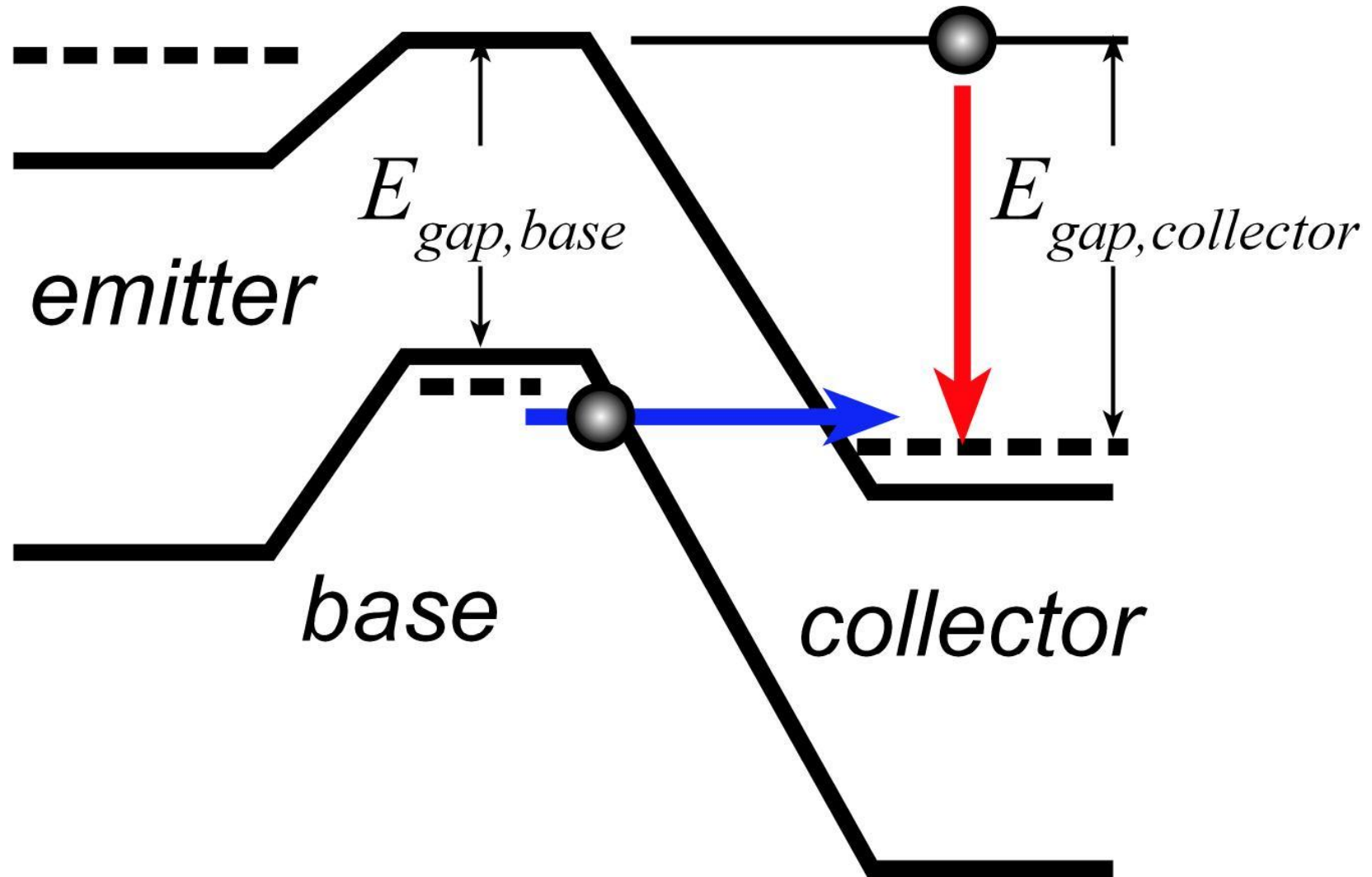
$$I_{c,max} \propto v_{sat} A_e (V_{ce,operating} + V_{ce,punch-through}) / T_c^2$$

$$\Delta T \propto \frac{P}{L_E} \left[1 + \ln \left(\frac{L_e}{W_e} \right) \right]$$

$$R_{ex} = \rho_{contact} / A_e$$

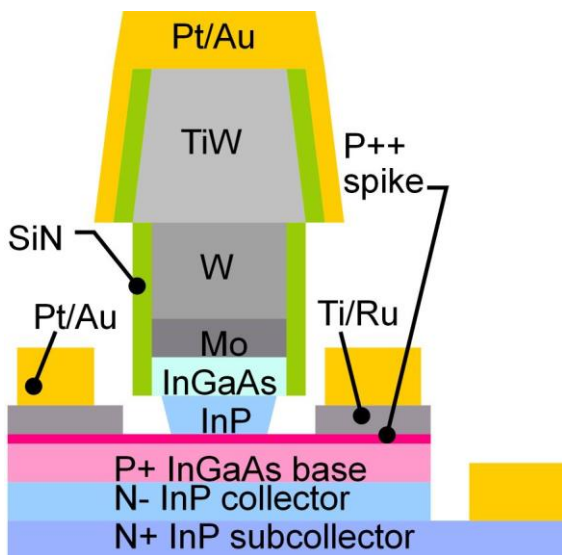
$$R_{bb} = \rho_{sheet} \left(\frac{W_e}{12L_e} + \frac{W_{bc}}{6L_e} \right) + \frac{\rho_{contact}}{A_{contacts}}$$

Energy-limited vs. field-limited breakdown



band-band tunneling: base bandgap
impact ionization: collector bandgap

Making faster bipolar transistors



to double the bandwidth:

to double the bandwidth:	change
emitter & collector junction widths	decrease 4:1
current density ($\text{mA}/\mu\text{m}^2$)	increase 4:1
current density ($\text{mA}/\mu\text{m}$)	constant
collector depletion thickness	decrease 2:1
base thickness	decrease 1.4:1
emitter & base contact resistivities	decrease 4:1

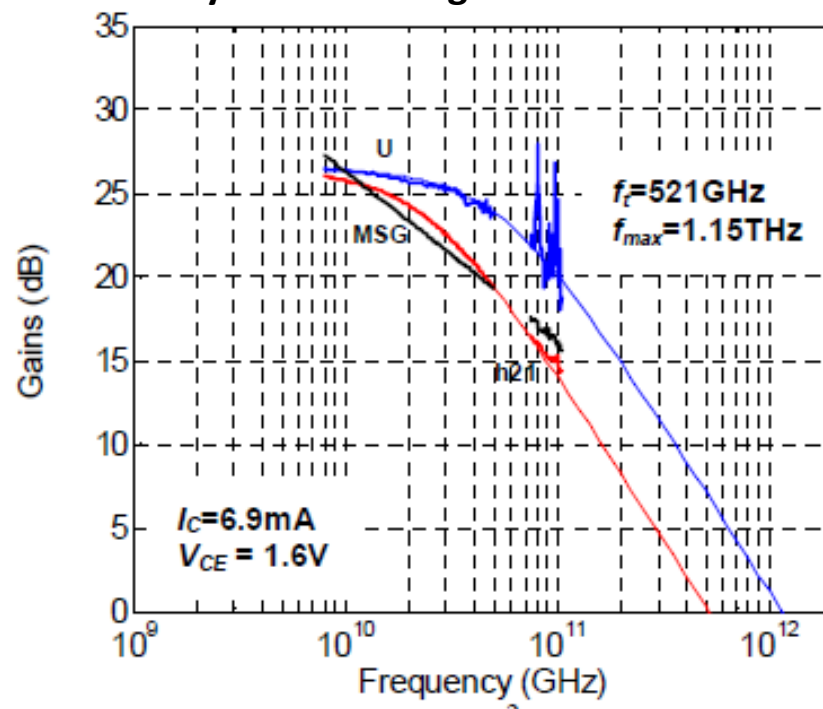
Narrow junctions.

Thin layers

High current density

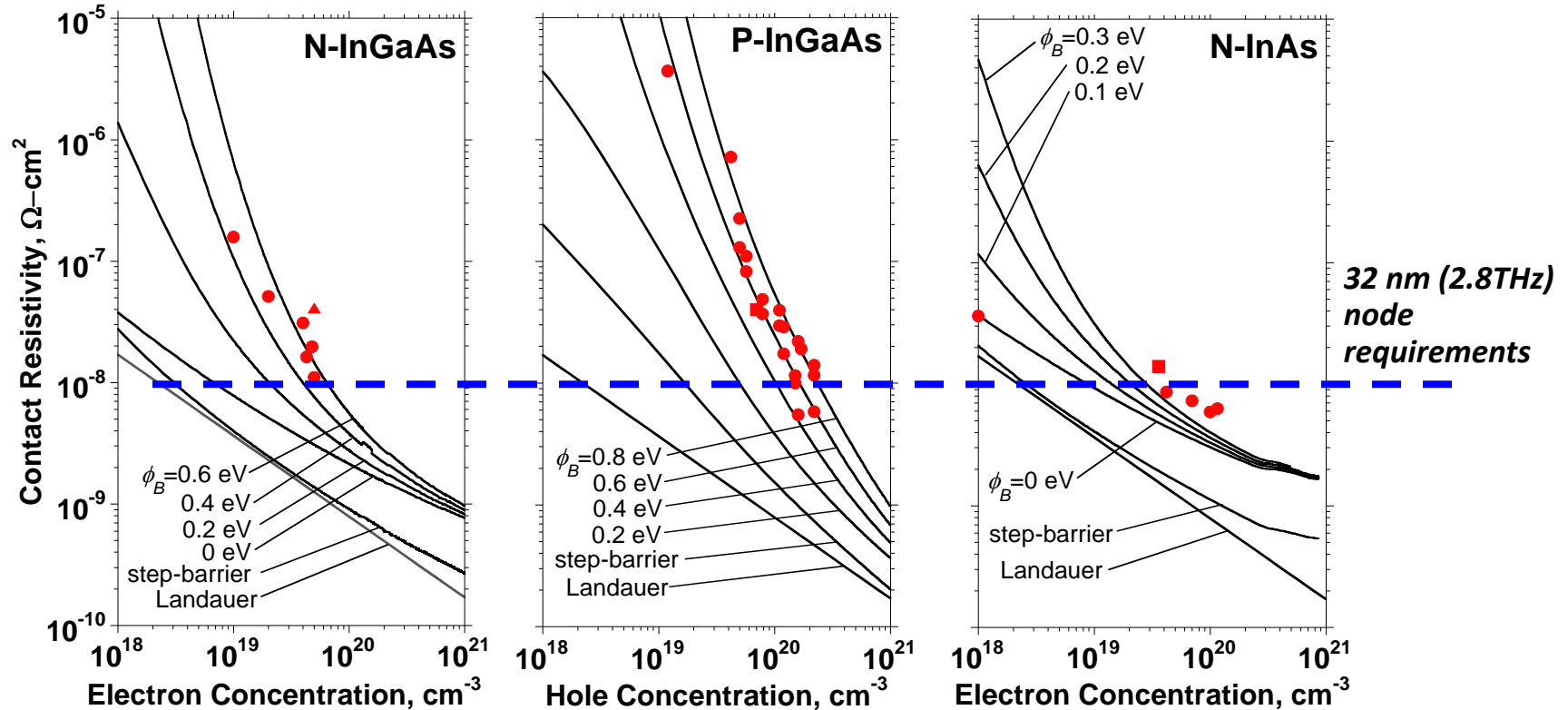
Ultra low resistivity contacts

Teledyne: M. Urteaga *et al*: 2011 DRC



Refractory Contacts to In(Ga)As

Baraskar *et al*, Journal of Applied Physics, 2013



Refractory: robust under high-current operation / Low penetration depth: ~ 1 nm / Performance sufficient for 32 nm / 2.8 THz node.

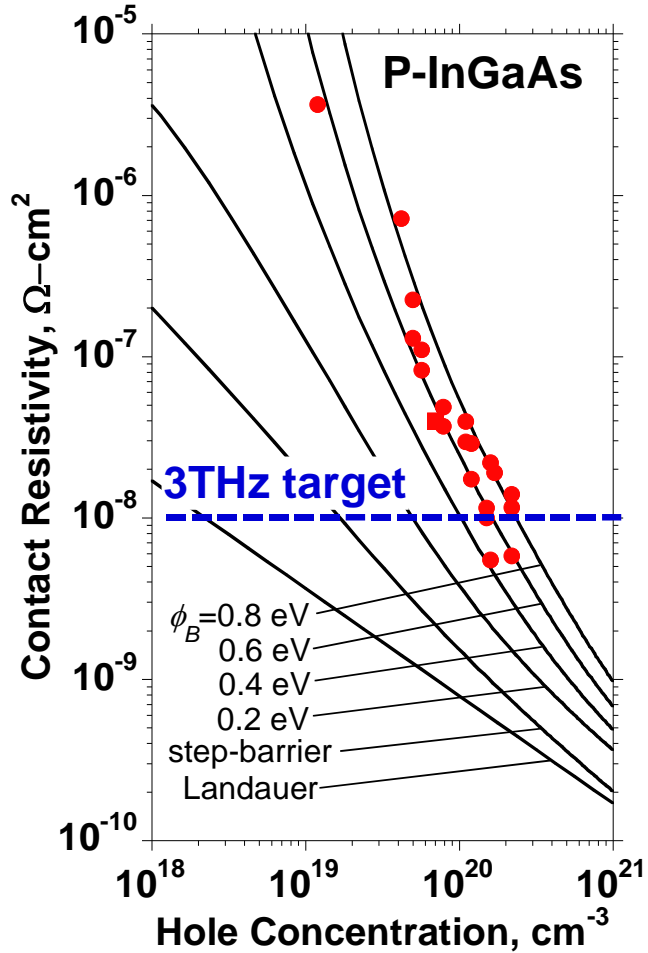
Why no ~ 2 THz HBTs today ?

Problem: reproducing these base contacts in full HBT process flow

THz HBTs: The key challenges

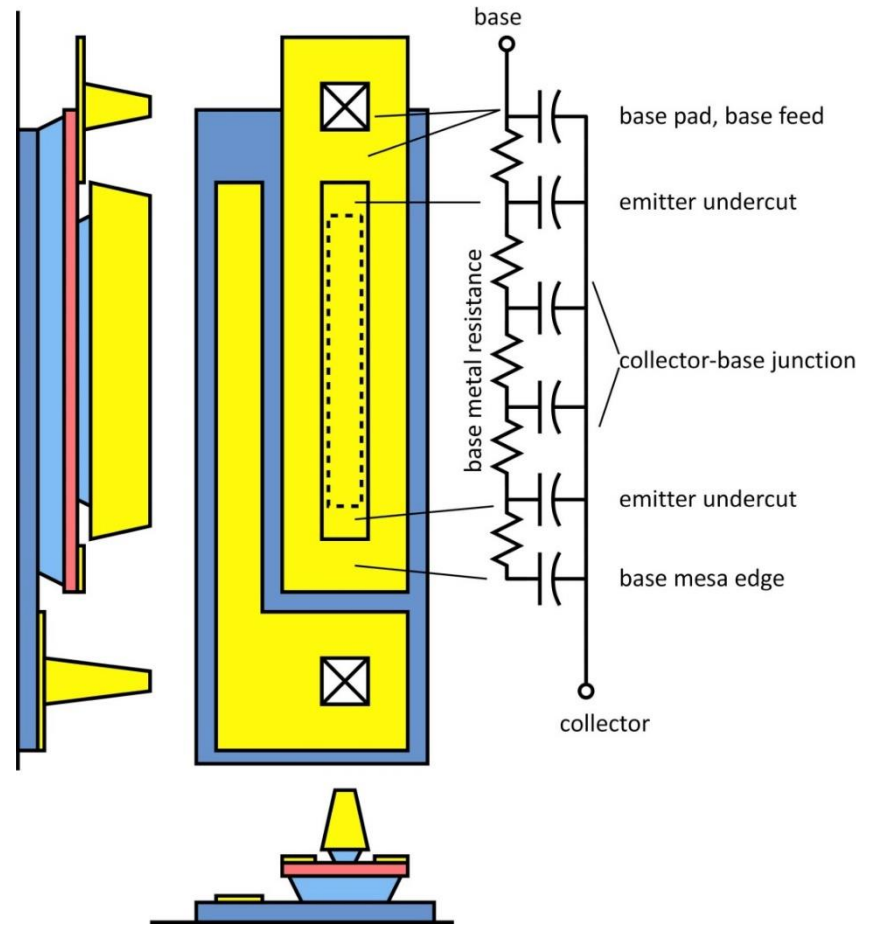
Obtaining good base contacts

in HBT vs. in contact test structure
(emitter contacts are fine)

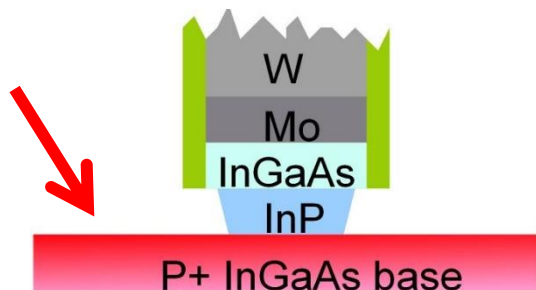


RC parasitics along finger length

metal resistance, excess junction areas

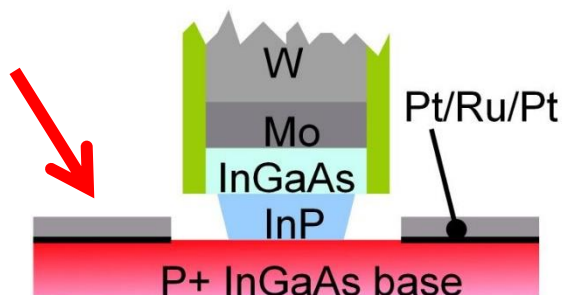


THz HBTs: double base metal process



Blanket surface clean (UV O₃ / HCl)

strips organics, process residues, surface oxides

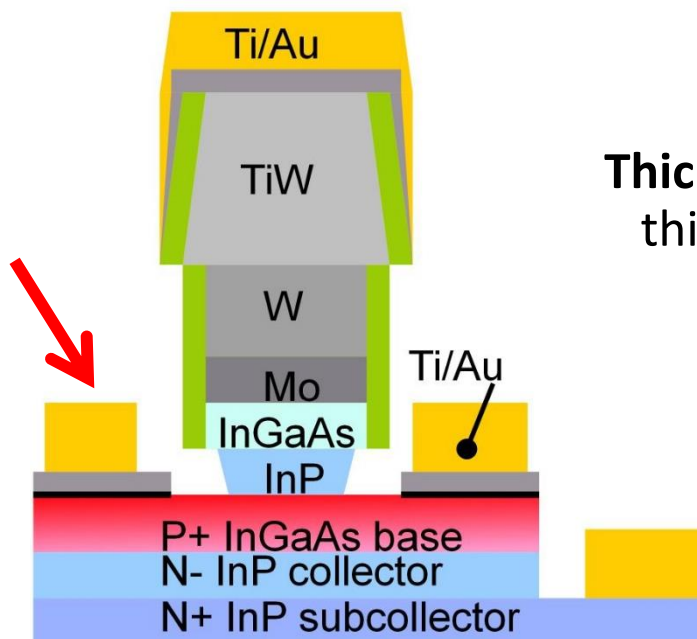


Blanket base metal

no photoresist; no organic residues

Ru refractory diffusion barrier

2 nm Pt : penetrates residual oxides

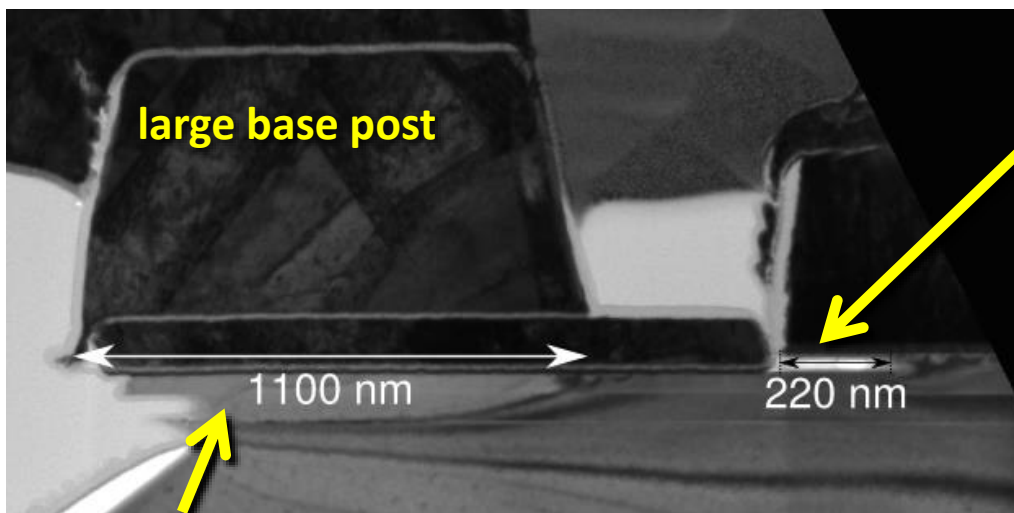


Thick Ti/Au base pad metal liftoff

thick metal → low resistivity

Reducing Emitter Length Effects

before



large base post

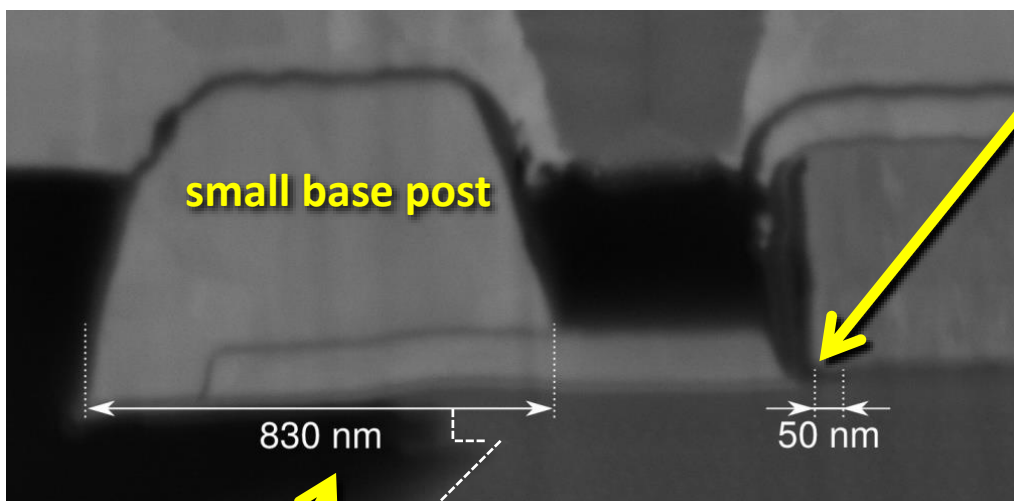
large emitter end undercut

1100 nm

220 nm

small base post undercut

after



small base post

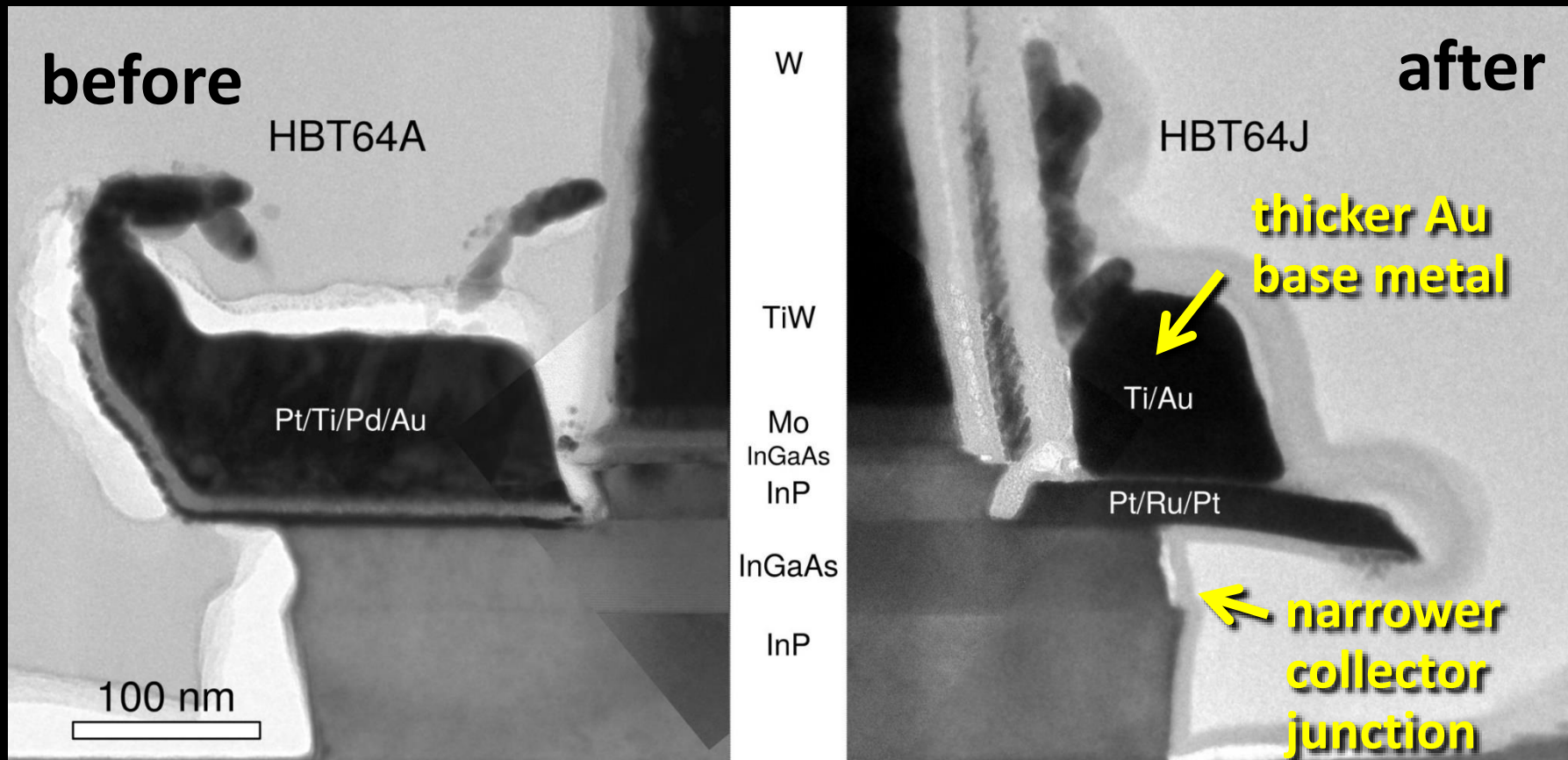
small emitter end undercut

830 nm

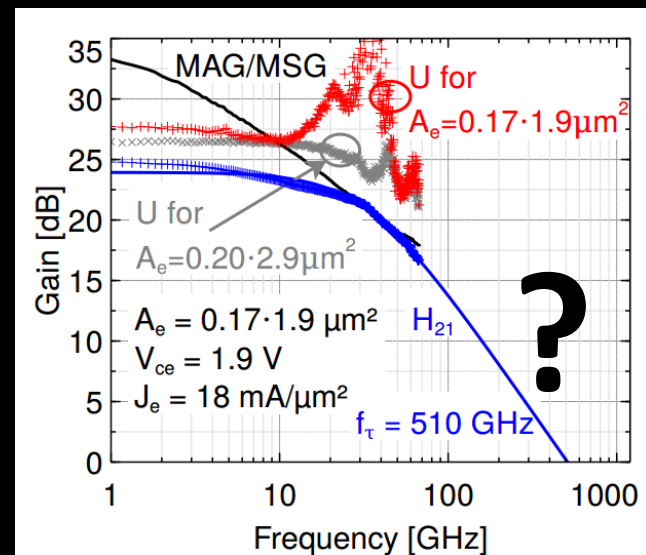
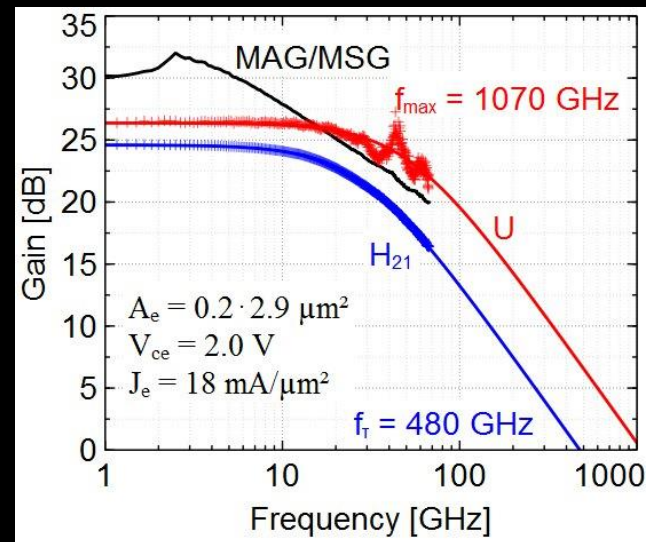
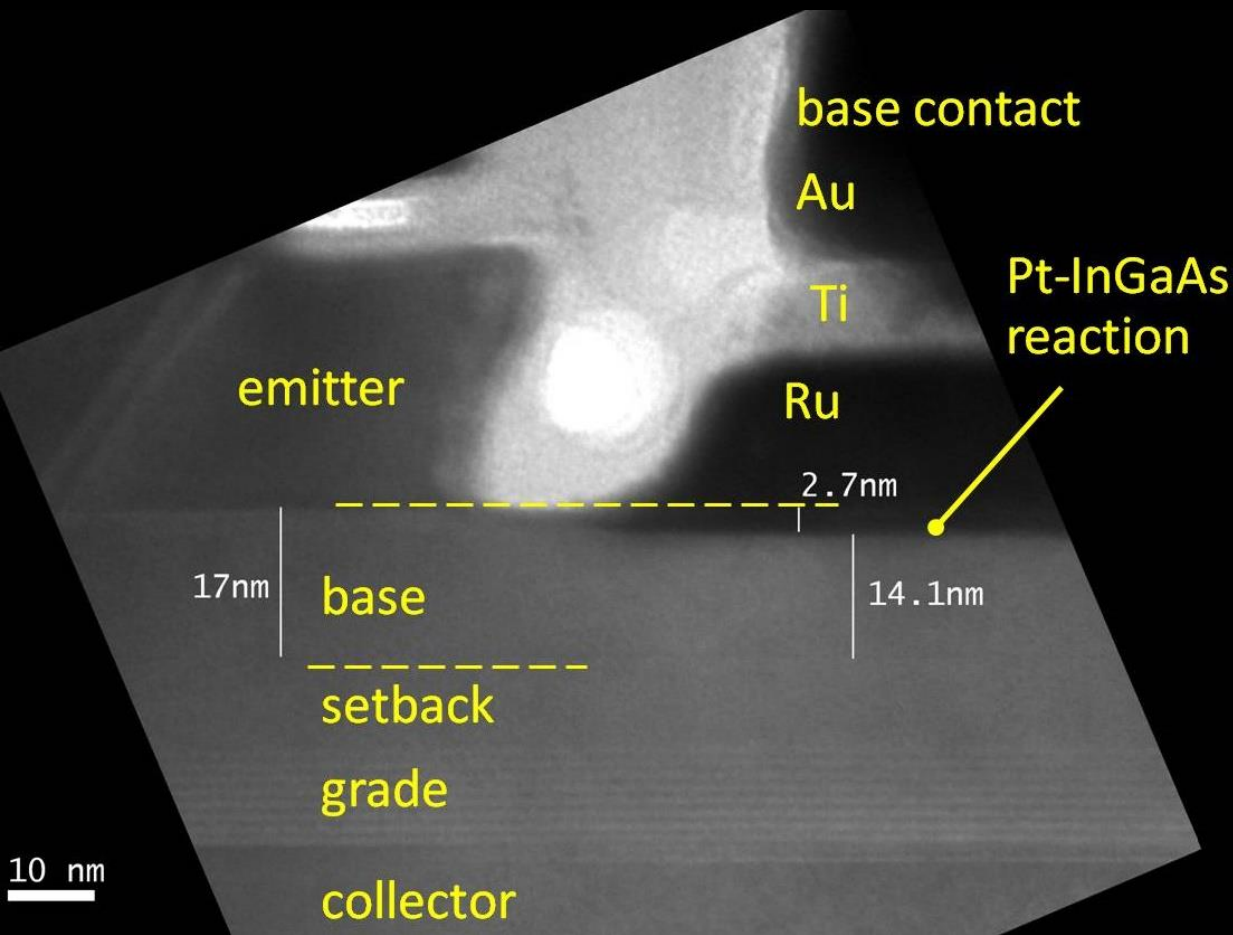
50 nm

large base post undercut

Reducing Emitter Length Effects

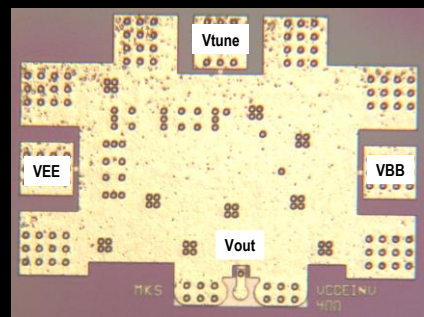


InP HBTs: 1.07 THz @200nm, ?? @ 130nm

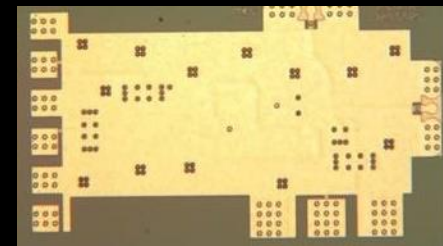


130nm / 1.1 THz InP HBT: ICs to 670 GHz

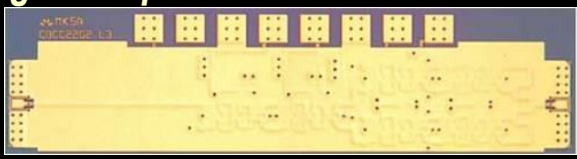
**614 GHz
fundamental
VCO**
M. Seo, TSC / UCSB



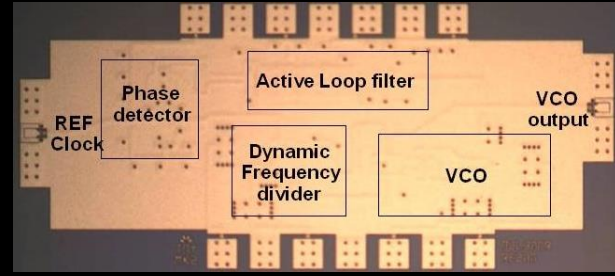
**340 GHz
dynamic
frequency
divider**
M. Seo, UCSB/TSC
IMS 2010



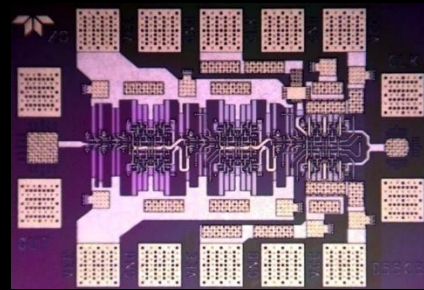
620 GHz, 20 dB gain amplifier
M Seo, TSC
IMS 2013
also: 670GHz amplifier
J. Hacker, TSC
IMS 2013 (not shown)



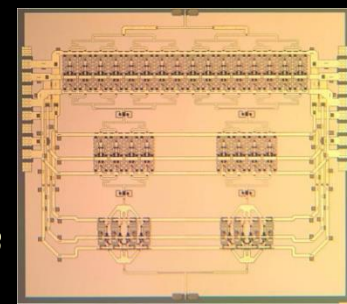
**300 GHz
fundamental
PLL**
M. Seo, TSC
IMS 2011



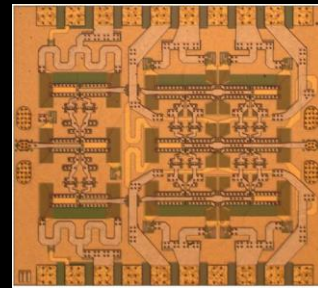
**204 GHz static
frequency divider
(ECL master-slave
latch)**
Z. Griffith, TSC
CSIC 2010



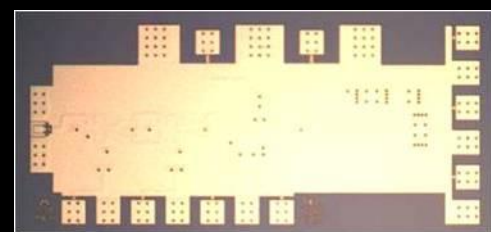
**220 GHz
180 mW
power
amplifier**
T. Reed, UCSB
CSICS 2013



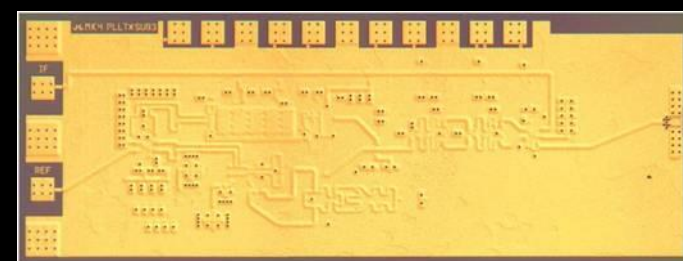
**81 GHz
470 mW
power
amplifier**
H-C Park UCSB
IMS 2014



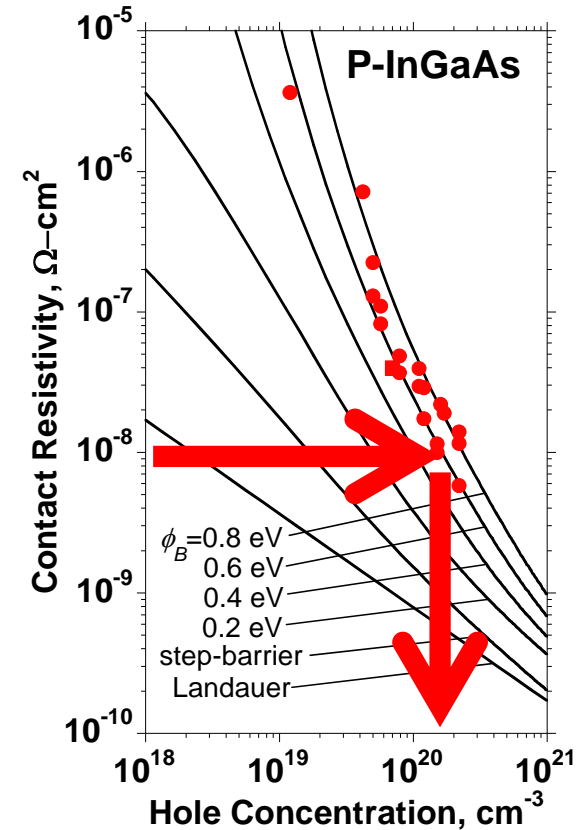
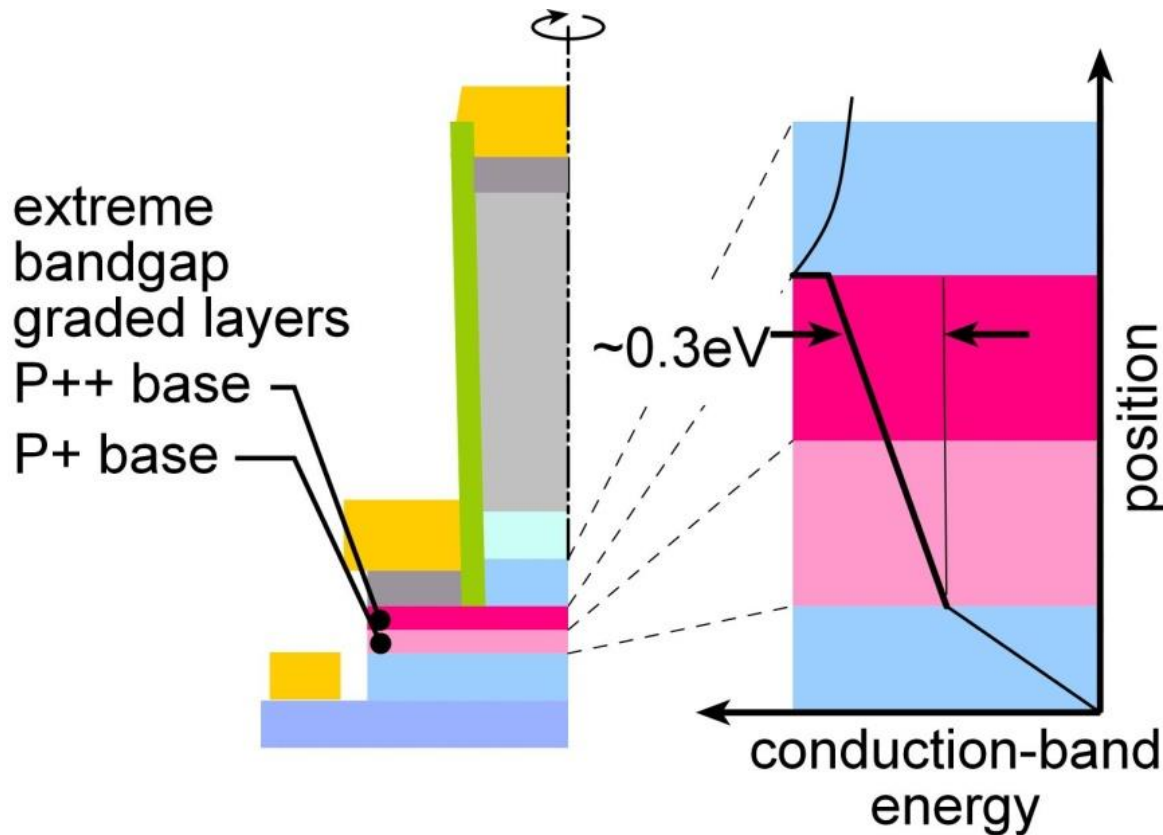
**Integrated
300/350GHz
Receivers:
LNA/Mixer/VCO**
M. Seo TSC



**600 GHz
Integrated
Transmitter
PLL + Mixer**
M. Seo TSC



Towards a 3 THz InP Bipolar Transistor



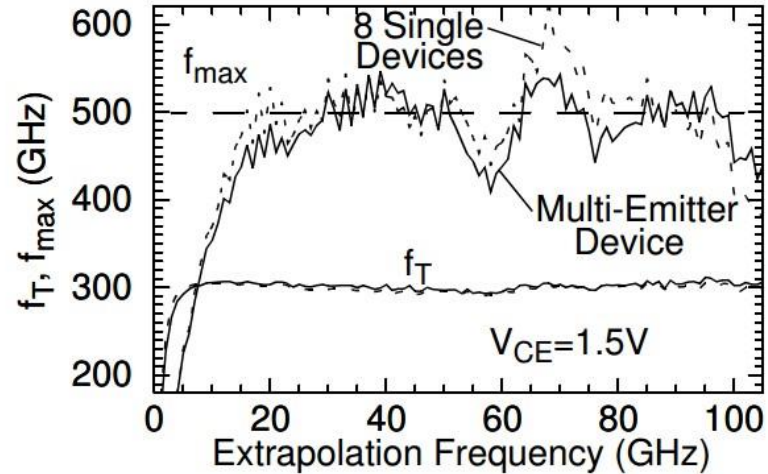
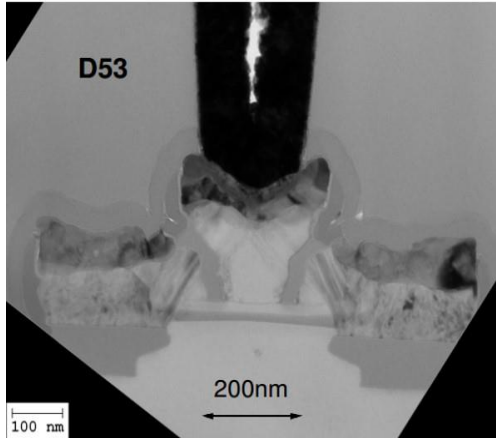
Extreme base doping \rightarrow low-resistivity contacts \rightarrow high f_{max}

Extreme base doping \rightarrow fast Auger ($N\text{P}^2$) recombination \rightarrow low β .

Solution: very strong base compositional grading \rightarrow high β

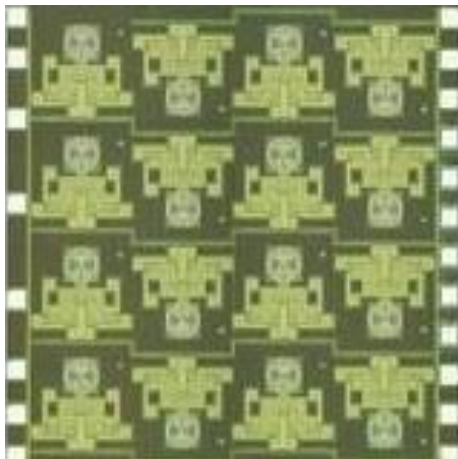
1/2-THz SiGe HBTs

500 GHz f_{\max} SiGe HBTs Heinemann et al. (IHP), 2010 IEDM



16-element multiplier array @ 500GHz (1 mW total output)

U. Pfeiffer et. al. (Wuppertal / IHP), 2014 ISSCC



Towards a 2 THz SiGe Bipolar Transistor

Similar scaling

InP: 3:1 higher collector velocity

SiGe: good contacts, buried oxides

Key distinction: Breakdown

InP has:

thicker collector at same f_{τ} ,
wider collector bandgap

Key requirements:

low resistivity Ohmic contacts

note the high current densities

	InP	SiGe	
emitter			
junction width	64	18	nm
access resistivity	2	0.6	$\Omega\text{-}\mu\text{m}^2$
base			
contact width	64	18	nm
contact resistivity	2.5	0.7	$\Omega\text{-}\mu\text{m}^2$
collector			
thickness	53	15	nm
current density	36	125	$\text{mA}/\mu\text{m}^2$
breakdown	2.75	1.3?	V
f_{τ}	1000	1000	GHz
f_{max}	2000	2000	GHz

Assumes collector junction 3:1 wider than emitter.

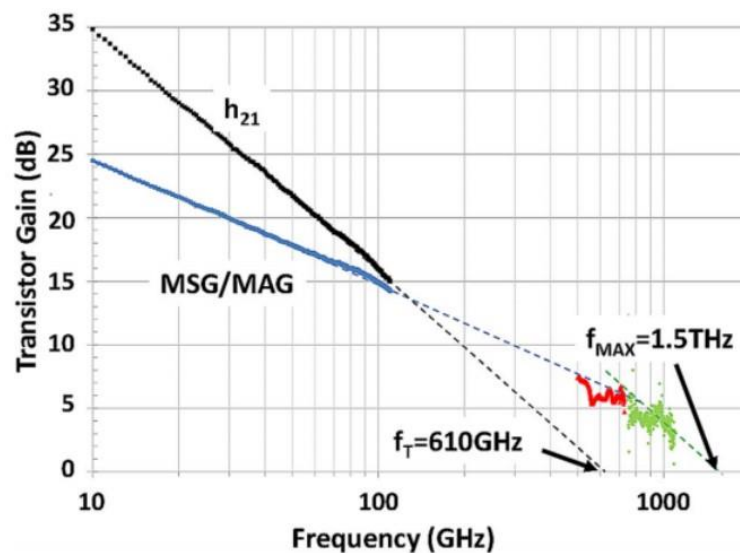
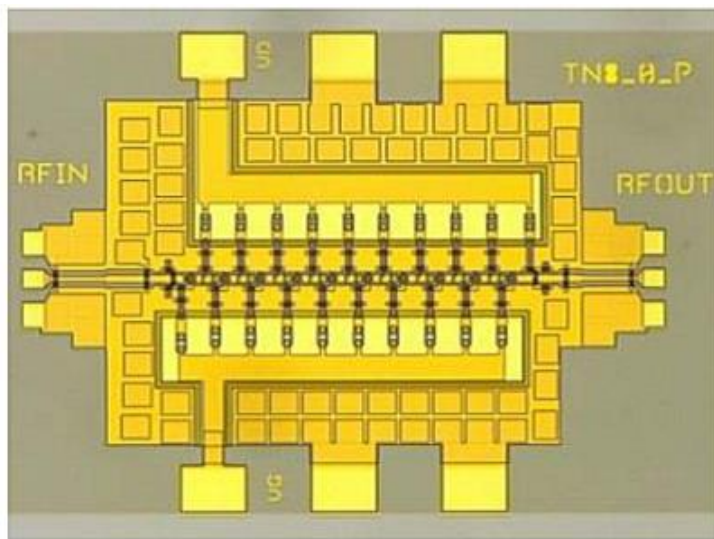
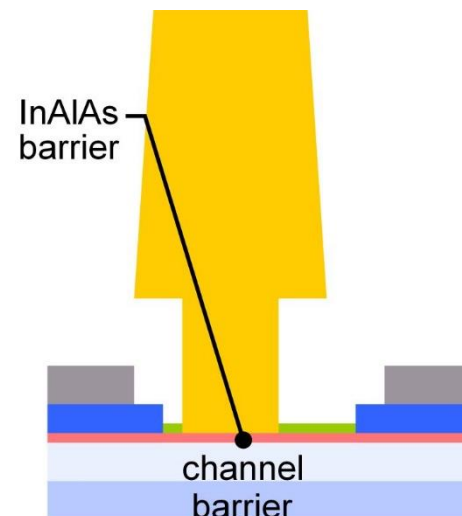
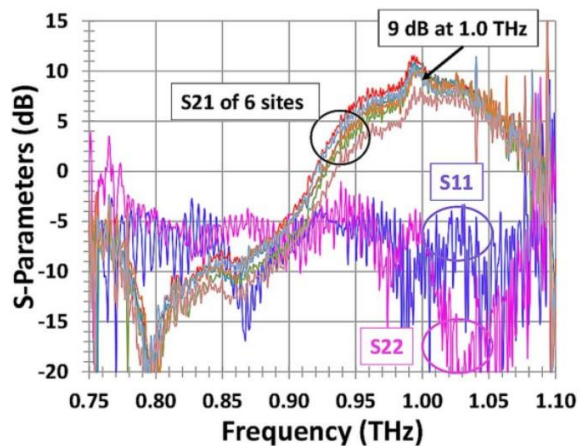
Assumes SiGe contacts no wider than junctions

InP Field-Effect Transistors

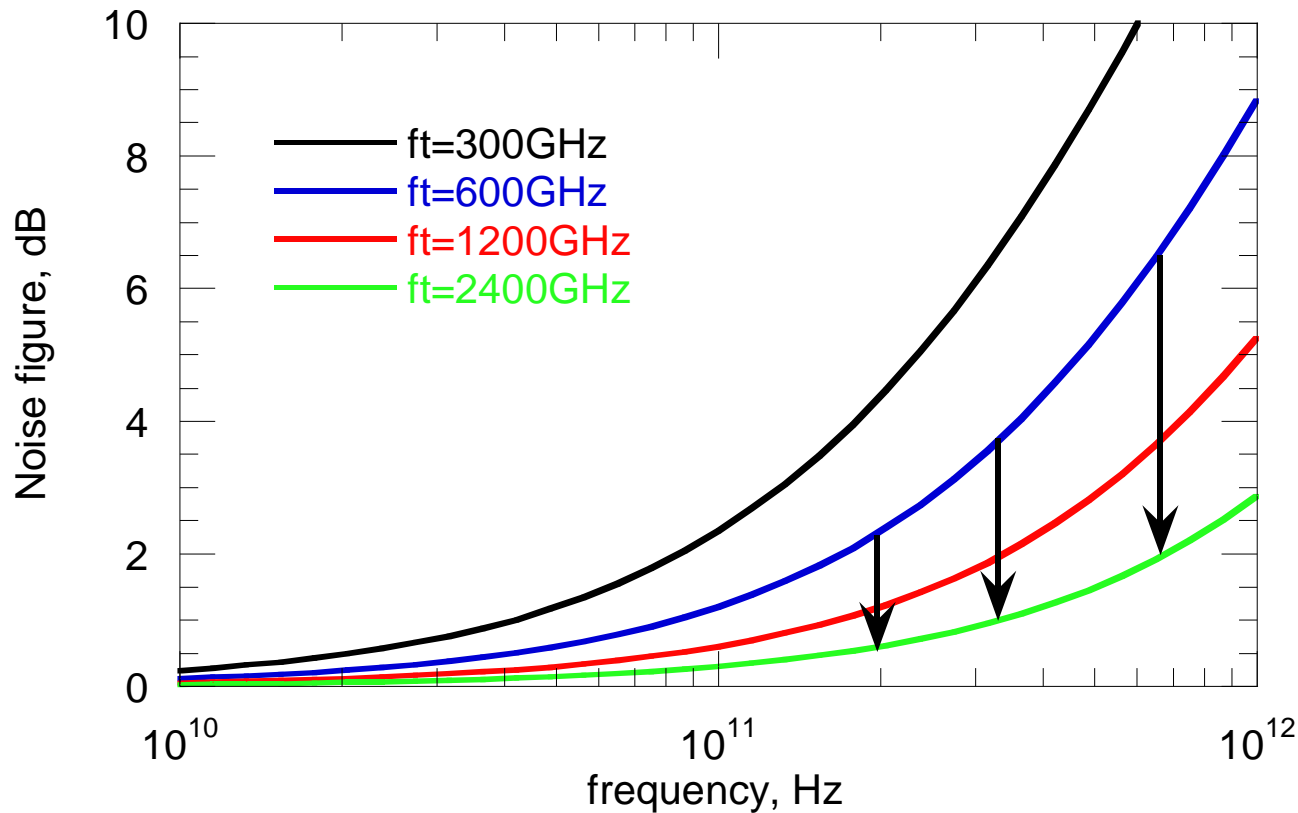
State of the art in InP HEMTs

First Demonstration of Amplification at 1 THz Using 25-nm InP High Electron Mobility Transistor Process

Xiaobing Mei, et al, IEEE EDL, April 2015 (Northrop-Grumman)



HEMTs: Key Device for Low Noise Figure



$$F_{\min} \approx 1 + 2\sqrt{g_m(R_s + R_g + R_i)\Gamma} \cdot \left(\frac{f}{f_\tau}\right) + 2g_m(R_s + R_g + R_i)\Gamma \cdot \left(\frac{f}{f_\tau}\right)^2$$

$$\Gamma \approx 1$$

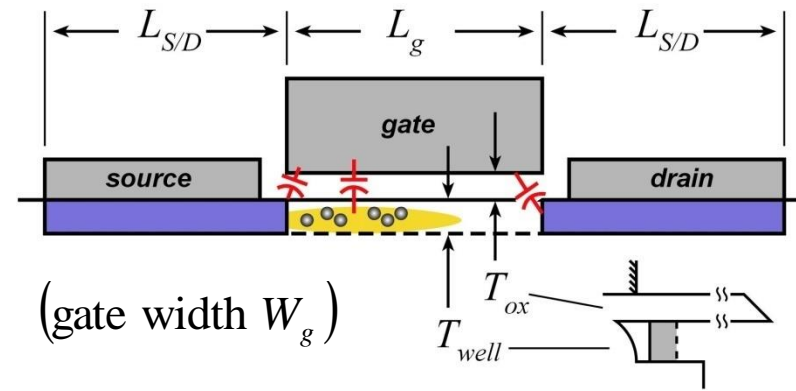
Hand-derived modified Fukui Expression, fits CAD simulation extremely well.

2:1 to 4:1 increase in $f_\tau \rightarrow$ greatly improved noise @ 200-670 GHz.

Better range in sub-mm-wave systems; or use smaller power amps.

or enable yet higher-frequency systems

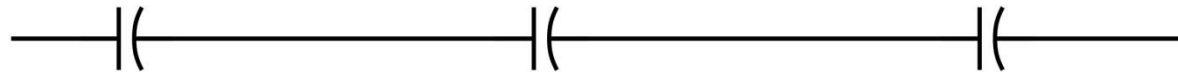
FET Design



$$C_{gd} \cong C_{gs,f} \cong \epsilon W_g$$

$$g_m = C_{g-ch} \cdot (v / L_g)$$

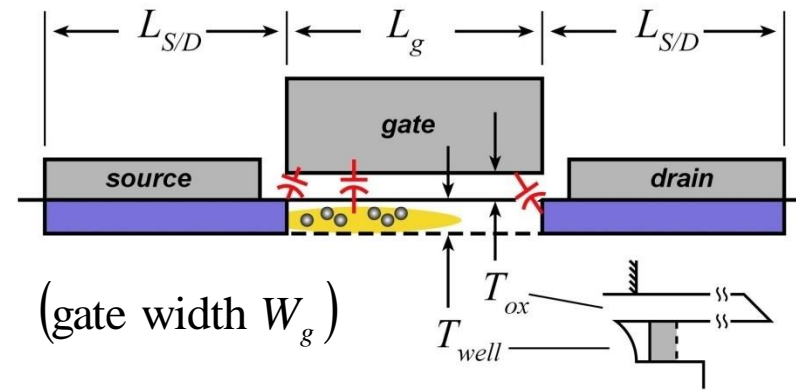
$$C_{g-ch} = \frac{L_g W_g}{T_{ox} / \epsilon_{ox} + T_{well} / 2\epsilon_{well} + (q^2 / \text{well state density})}$$



$$v \propto \left(\text{voltage division ratio between the above three capacitors} \right)^{-1/2} \cdot \frac{1}{\sqrt{\text{transport mass}}}$$

$$R_{DS} \approx L_g / (W_g v \epsilon) \quad R_S = R_D = \frac{\rho_{\text{contact}}}{L_{S/D} W_g}$$

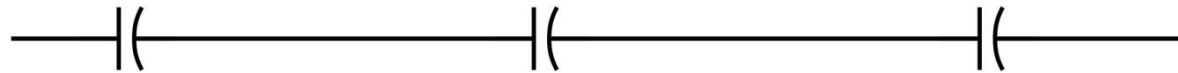
FET Design: Scaling



$$C_{gd} \cong C_{gs,f} \cong \epsilon W_g$$

$$g_m = C_{g-ch} \cdot (v / L_g)$$

$$C_{g-ch} = \frac{L_g W_g}{T_{ox} / \epsilon_{ox} + T_{well} / 2\epsilon_{well} + (q^2 / \text{well state density})}$$

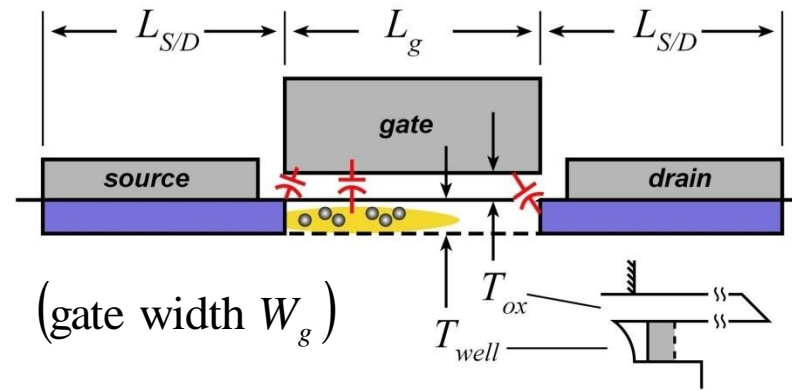


$$v \propto \left(\text{voltage division ratio between the above three capacitors} \right)^{-1/2} \cdot \frac{1}{\sqrt{\text{transport mass}}}$$

$$R_{DS} \approx L_g / (W_g v \epsilon)$$

$$R_S = R_D = \frac{\rho_{\text{contact}}}{L_{S/D} W_g}$$

FET Design: Scaling



$$2:1 \downarrow C_{gd} \cong C_{gs,f} \cong \epsilon W_g \quad 2:1 \downarrow$$

$$\text{constant } g_m = C_{g-ch} \cdot (v / L_g) \quad 2:1 \downarrow$$

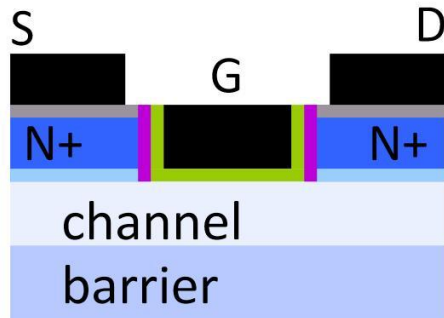
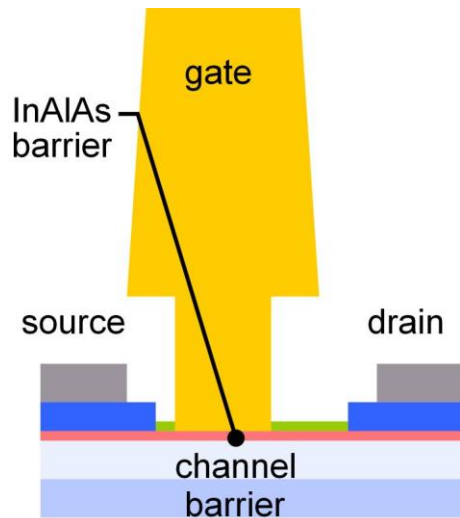
$$C_{g-ch} = \frac{L_g W_g}{\frac{T_{ox}}{\epsilon_{ox}} + \frac{T_{well}}{2\epsilon_{well}} + (q^2 / \text{well state density})}$$

$$v \propto \left(\text{voltage division ratio between the above three capacitors} \right)^{-1/2} \cdot \frac{1}{\sqrt{\text{transport mass}}}$$

$$\text{constant } R_{DS} \approx L_g / (W_g v \epsilon)$$

$$\text{constant } R_S = R_D = \frac{\rho_{\text{contact}}}{L_{S/D} W_g}$$

FET Scaling Laws (these now broken)

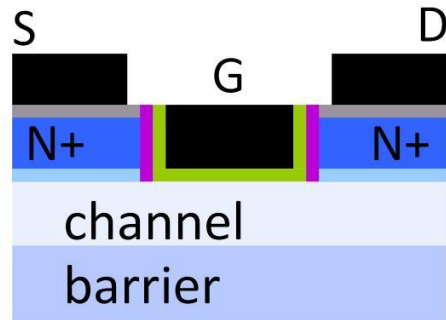
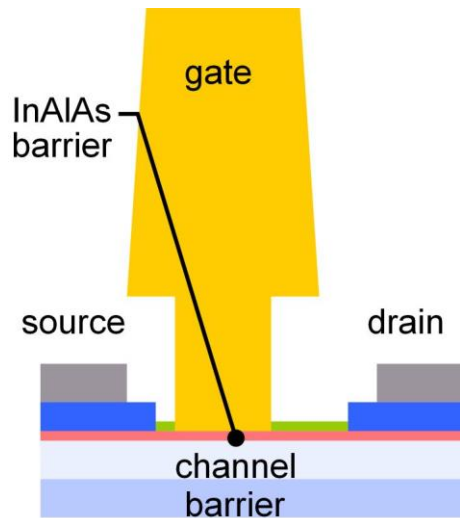


- vertical S/D spacer
- low-K dielectric spacer
- high-K gate dielectric

FET parameter	change
gate length	decrease 2:1
current density (mA/mm)	increase 2:1
transport mass	constant
2DEG electron density	increase 2:1
gate-channel capacitance density	increase 2:1
dielectric equivalent thickness	decrease 2:1
channel thickness	decrease 2:1
channel state density	increase 2:1
contact resistivities	decrease 4:1

fringing capacitance does not scale → linewidths scale as $(1 / \text{bandwidth})$

FET Scaling Laws (these now broken)



- vertical S/D spacer
- low-K dielectric spacer
- high-K gate dielectric

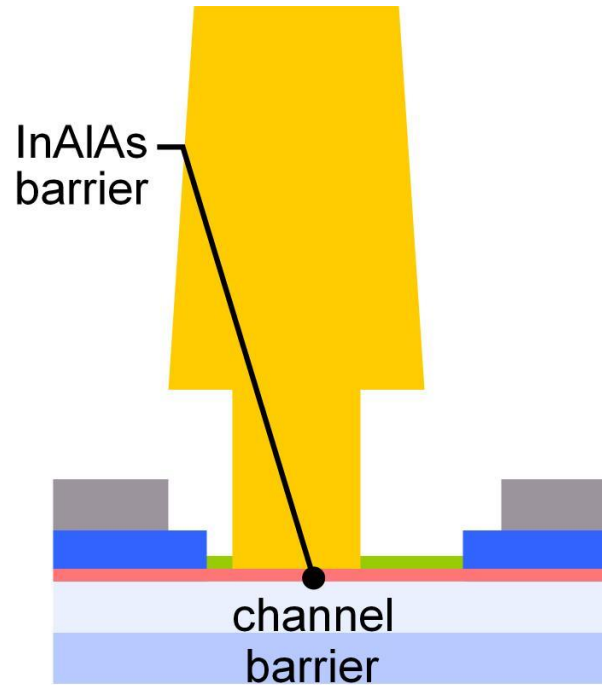
FET parameter	change
gate length	decrease 2:1
current density (mA/mm)	increase 2:1
transport mass	constant
2DEG electron density	increase 2:1
gate-channel capacitance density	increase 2:1
dielectric equivalent thickness	decrease 2:1
channel thickness	decrease 2:1
channel state density	increase 2:1
contact resistivities	decrease 4:1

**Gate dielectric can't be much further scaled.
Not in CMOS VLSI, not in mm-wave HEMTs**

**g_m/W_g (mS/ μm) hard to increase
 $\rightarrow C_{end}/g_m$ prevents f_τ scaling.**

**Shorter gate lengths degrade electrostatics
 \rightarrow reduced $g_m/G_{ds} \rightarrow$ reduced f_{max}/f_τ**

Why THz HEMTs no longer scale



HEMTs: gate barrier also lies under S/D contacts → high S/D access resistance

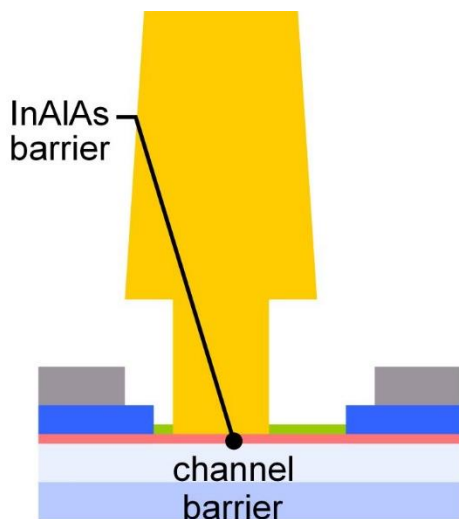
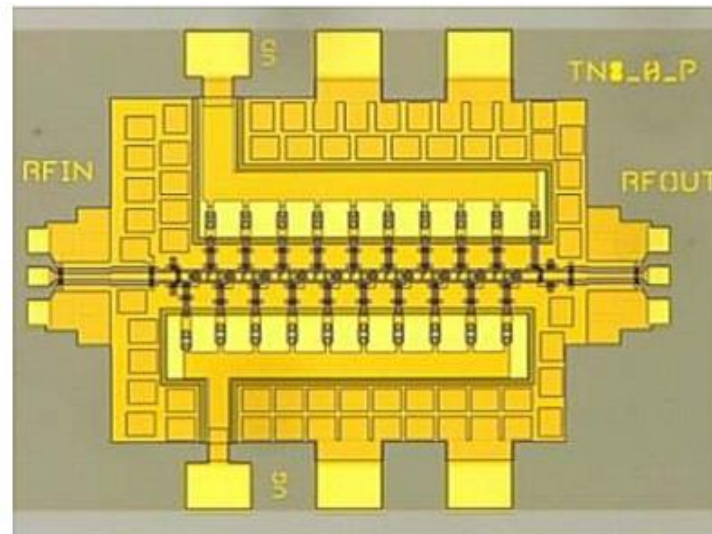
As gate length is scaled, gate barrier must be thinned for high g_m , low G_{ds}

HEMTs: High gate leakage when gate barrier is thinned → cannot thin barrier

Towards at 2.5 THz HEMT

First Demonstration of Amplification at 1 THz Using 25-nm InP High Electron Mobility Transistor Process

Xiaobing Mei, et al, IEEE EDL, April 2015 (Northrop-Grumman)

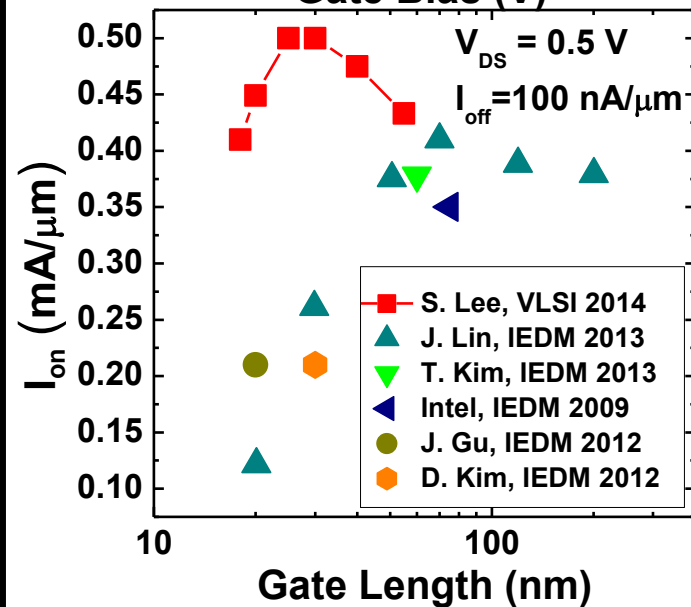
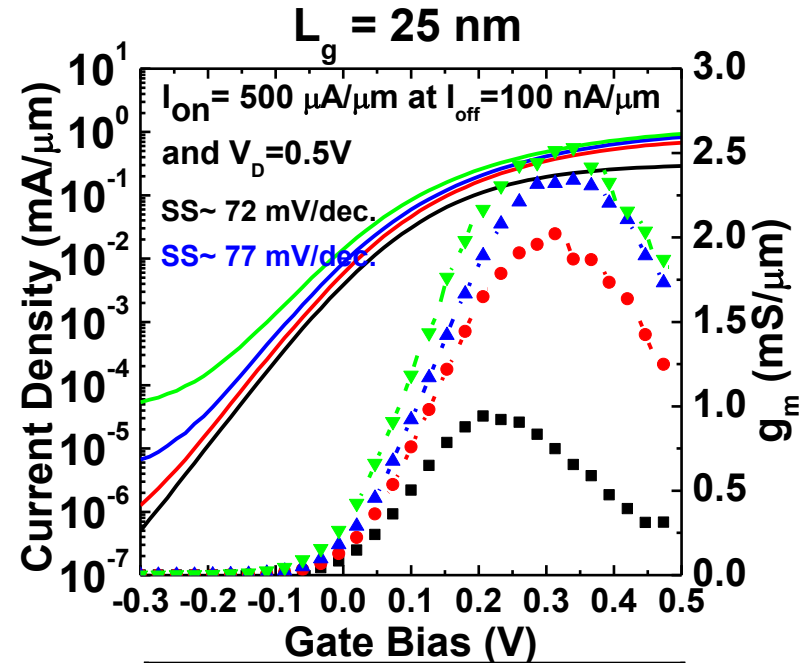
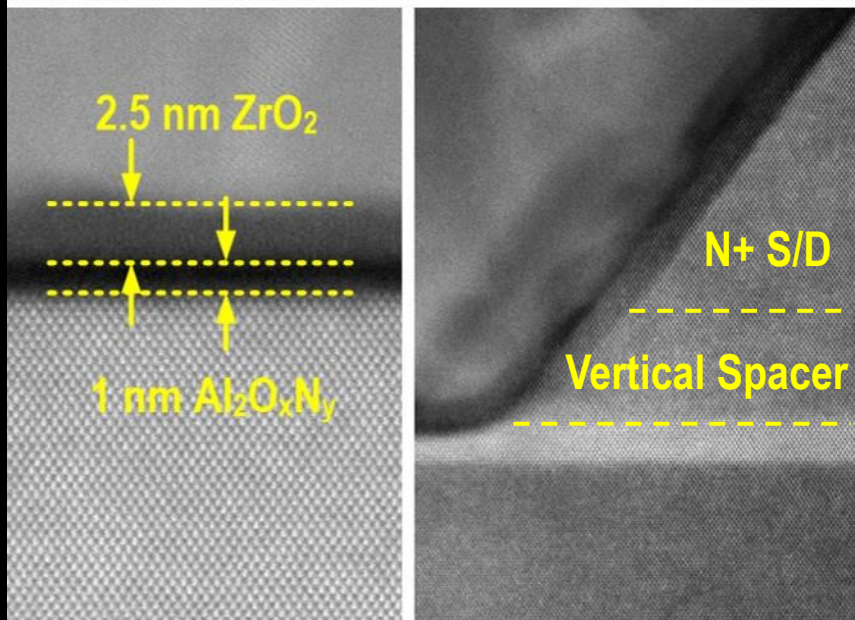
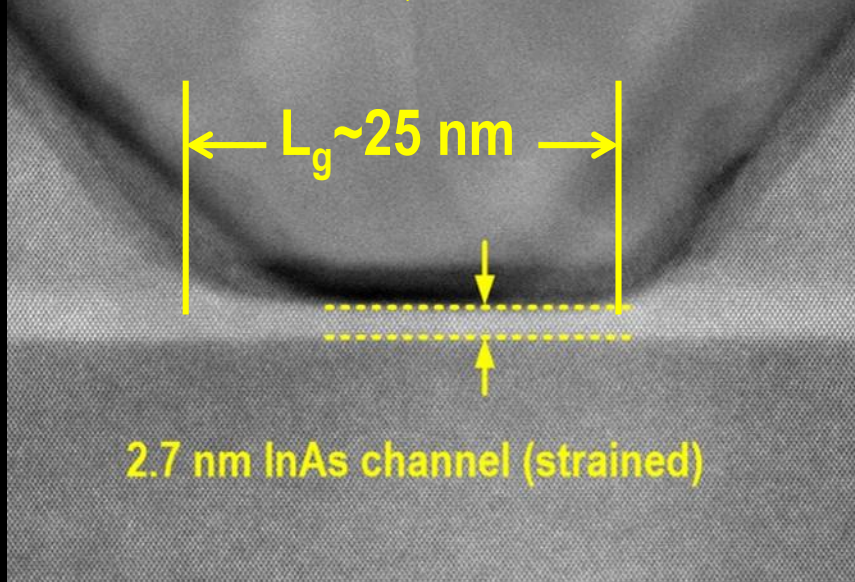


FET scaling laws; 2:1 higher bandwidth	change
gate length	decrease 2:1
current density (mA/mm), g_m (mS/mm)	increase 2:1
transport mass	constant
gate-channel capacitance density	increase 2:1
contact resistivities	decrease 4:1

Need thinner dielectrics, better contacts

Record III-V MOS

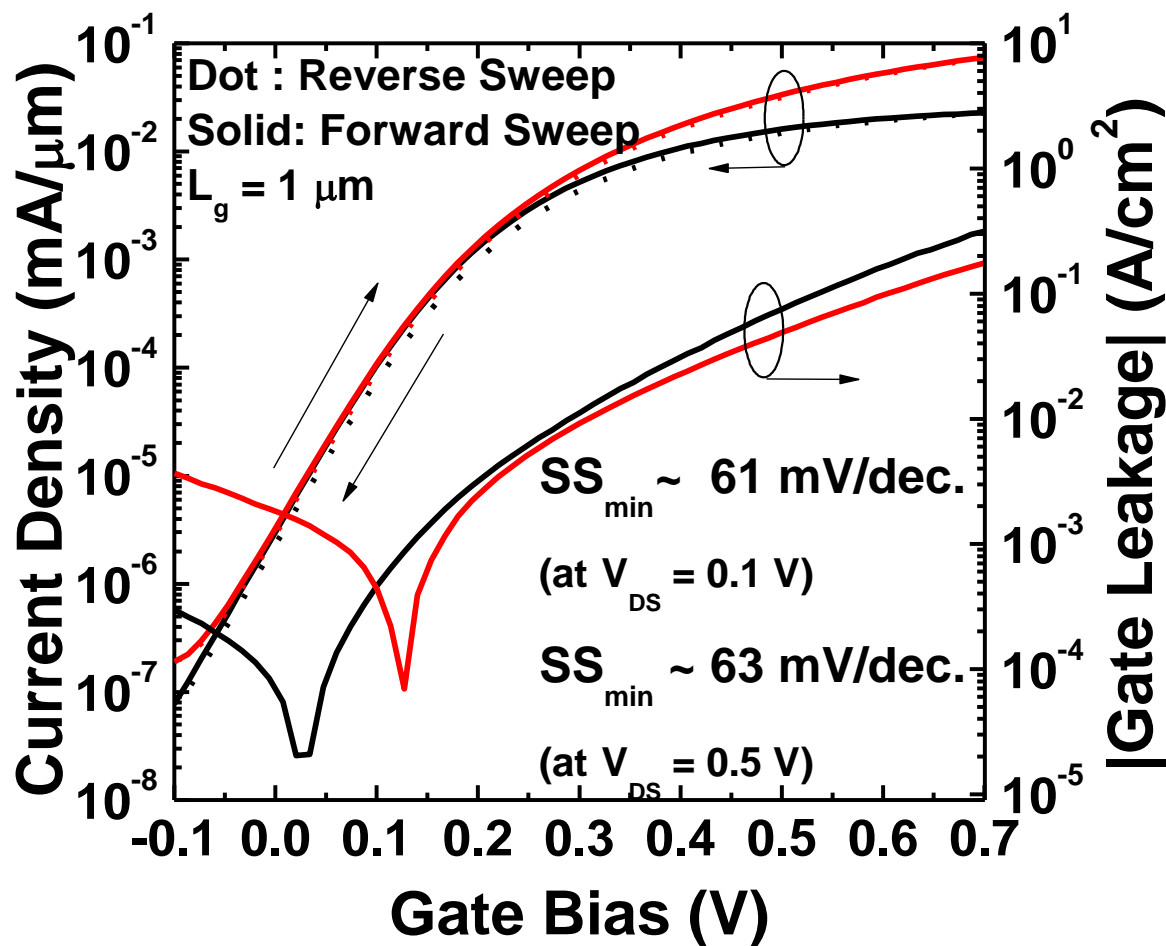
S. Lee et al., VLSI 2014



record for III-V

= best UTB SOI silicon

Excellent III-V gate dielectrics



2.5nm ZrO_2
1nm Al_2O_3
2.5nm InAs

V. Chobpattanna,
S. Stemmer

FET data: S Lee, 2014 VLSI Symp.

61 mV/dec Subthreshold swing at $V_{DS}=0.1 \text{ V}$
Negligible hysteresis

III-V MOS @ $L_g = ???$

N+ InGaAs

$L_g \sim 12\text{nm}$

N+ InP

$\sim 8\text{nm}$

InP spacer

InAlAs
Barrier

$t_{ch} \sim 2.5\text{ nm}$

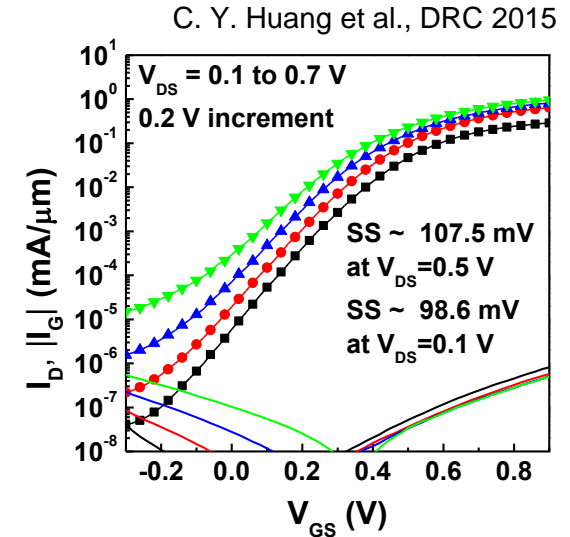
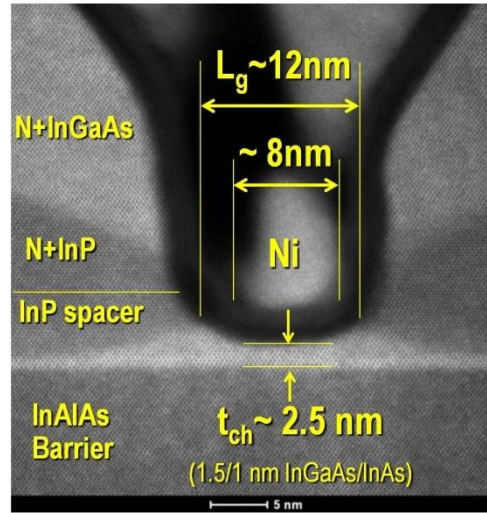
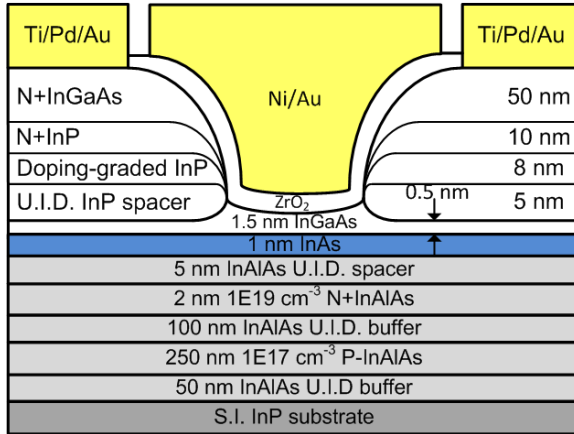
5 nm

Huang *et al.*,
2015 DRC

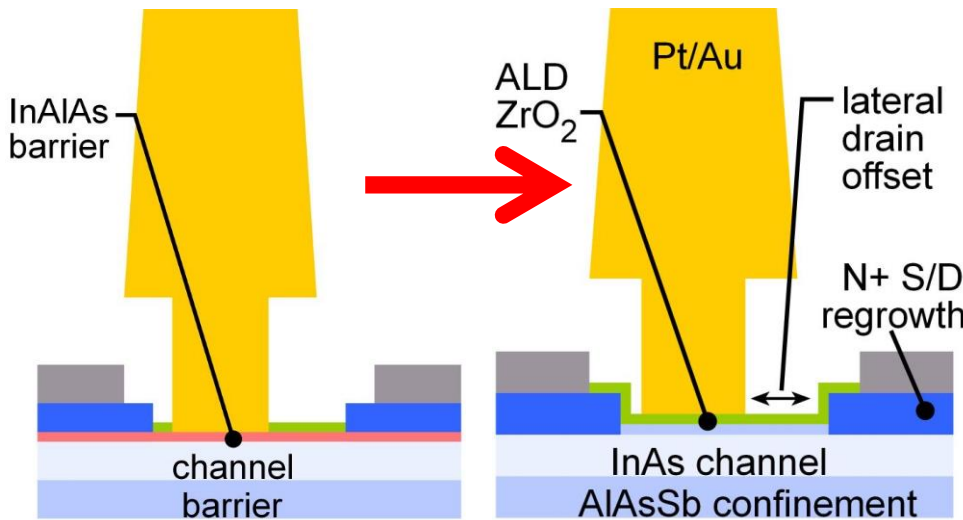
Image courtesy of
S. Kraemer (UCSB)

Towards at 2.5 THz HEMT

VLSI III-V MOS



THz III-V MOS



gate length	36	18	9	nm
EOT	0.8	0.4	0.2	nm
well thickness	5.6	2.8	1.4	nm
effective mass	0.05	0.08	0.08	times m_0
# bands	1	1	1	--
S/D resistivity	150	74	37	$\Omega\text{-}\mu\text{m}$
extrinsic g_m	2.5	4.2	6.4	$\text{mS}/\mu\text{m}$
on-current	0.55	0.8	1.1	$\text{mA}/\mu\text{m}$
f_T	0.70	1.2	2.0	THz
f_{max}	0.81	1.4	2.7	THz

mm-wave measurements

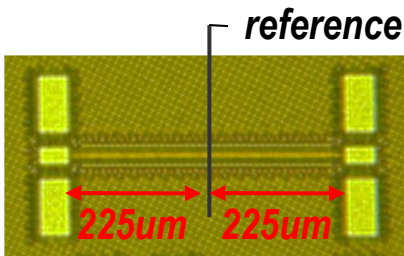
On-Wafer Network Analysis: 750+ GHz

- Agilent, Rhode/Schwarz network analyzer,
- *Oleson Microwave Lab* or *Virginia Diodes* frequency extenders
- micro-coax wafer probes with waveguide connections
GGB Industries,
Cascade Microtech
University of Virginia.
- Internal bias Tee's in probes
- Mostly on-wafer calibration standards.



On-Wafer Through-Reflect-Line (TRL) Calibration

Through



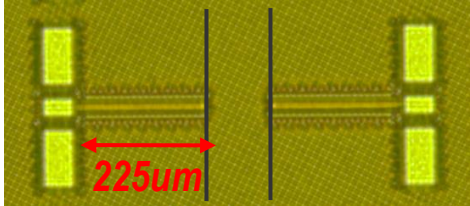
reference plane

225um 225um

*Through line should be long for large probe separation.
Minimizes probe-probe coupling.
Measurements normalized to the line characteristic impedance.*

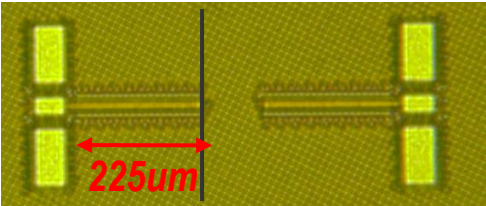
Reflect

open



225um

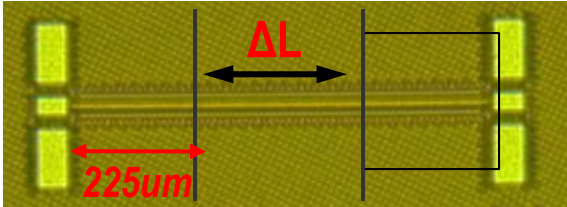
short



225um

*Either open or short needed.
Standards need not be accurate.
"Open" must have Γ closer to that of open than that of short.
Ports 1 & 2 must be symmetric.*

Line

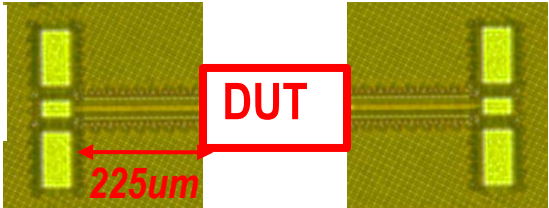


225um

ΔL

*$\Delta L = 90 \text{ deg @center frequency.}$
 $\lambda/8 < \Delta L < 3\lambda/8$*

Device Under Test



225um

DUT

Please see also:

http://www.ece.ucsb.edu/Faculty/rodwell/publications_and_presentations/publications/204vg.ppt

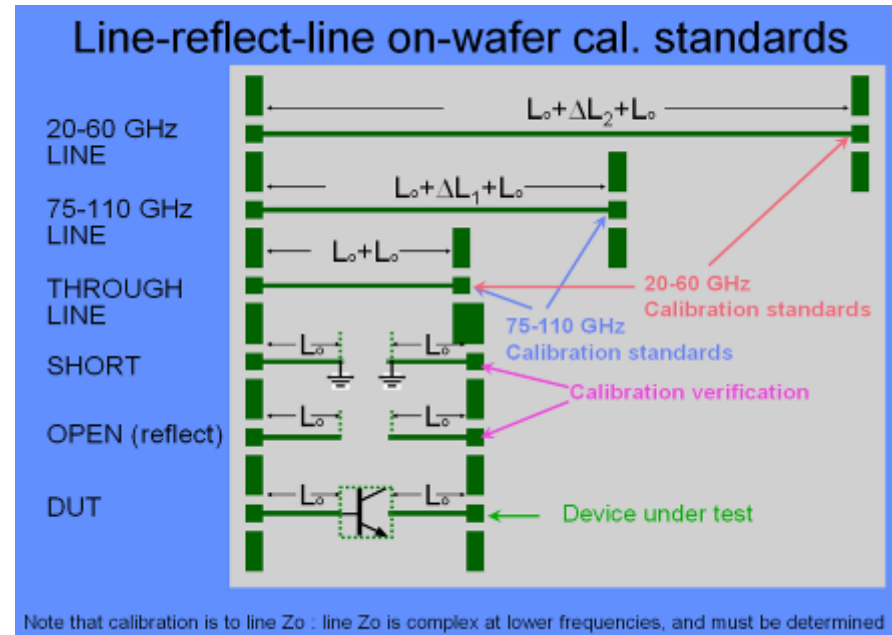
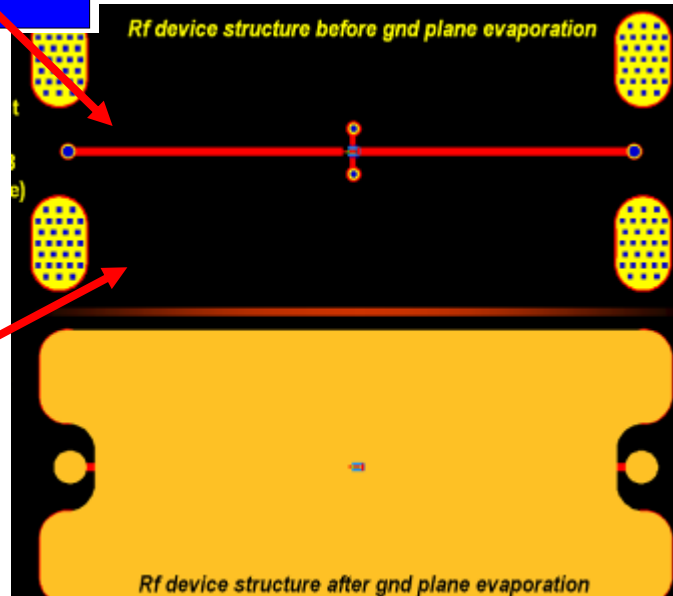
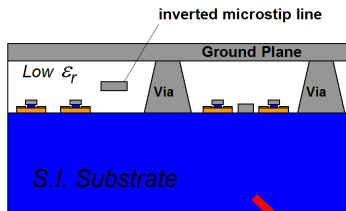
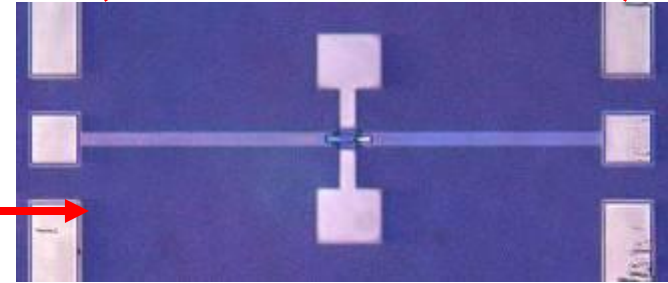
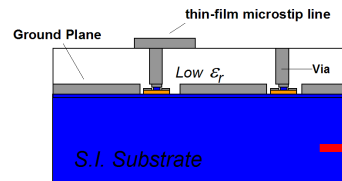
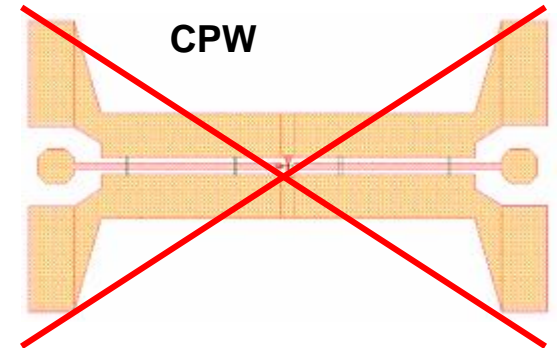
On-Wafer Line Reflect Line Calibration

Extended Reference planes

transistors placed at center of long on-wafer line
 LRL standards placed on wafer
 large probe separation → probe coupling reduced
 still should use the best-shielded probes available

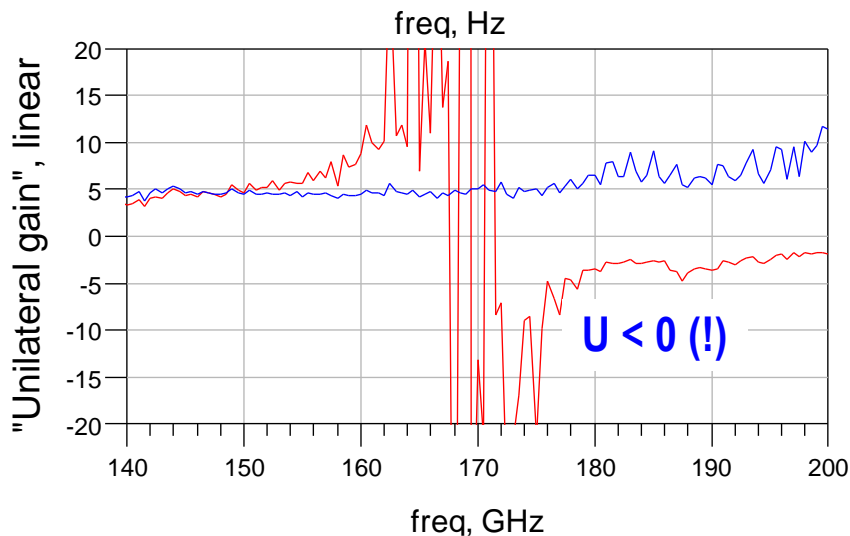
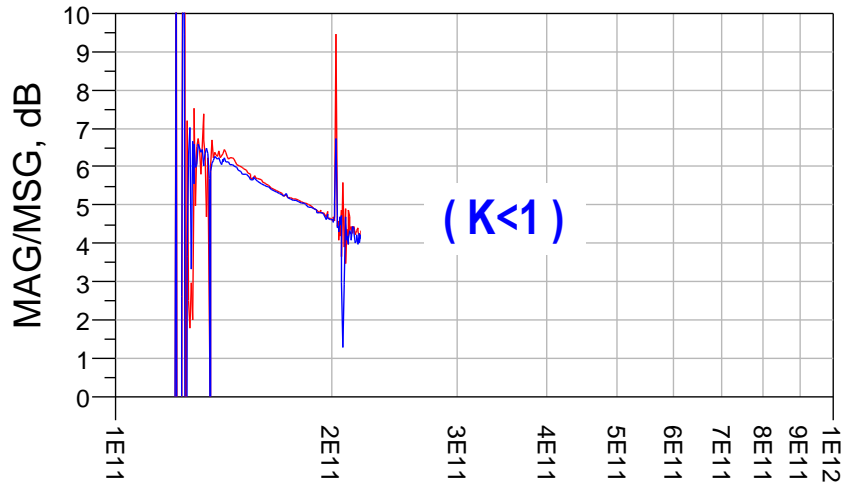
Problem: substrate mode coupling

method will FAIL if lines couple to substrate modes
 → method works very poorly with CPW lines
 need on wafer thin-film microstrip lines



Difficulties with >100 GHz On-Wafer Calibration

Data on two layouts of 65 nm MOSFET

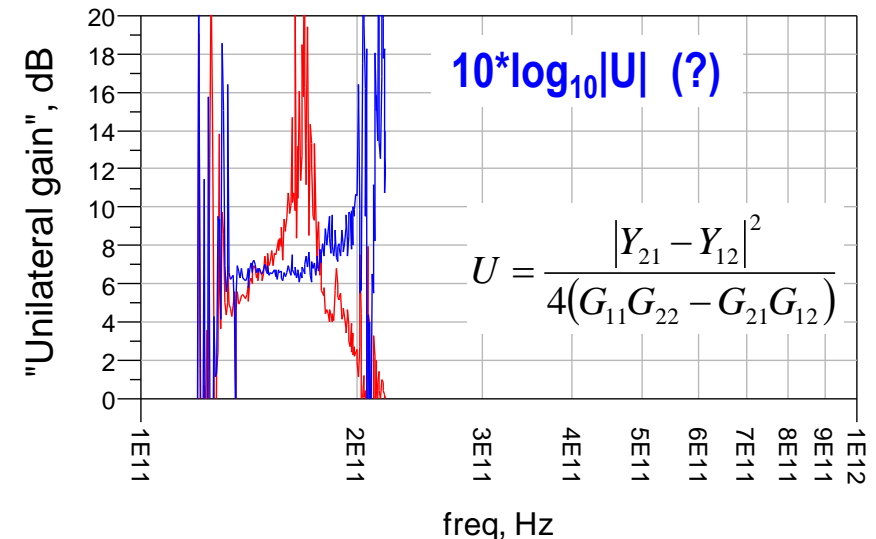


Measured Y-parameters correlate reasonably with expected device model.

Small errors in measured 2-port parameters result in large changes in Unilateral gain and Rollet's stability factor; neither measurement is credible.

Y_{12} appears to be the key problem.

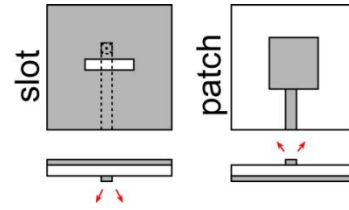
IC S_{ij} measurements are fine. Transistor f_{max} measurements are hard.



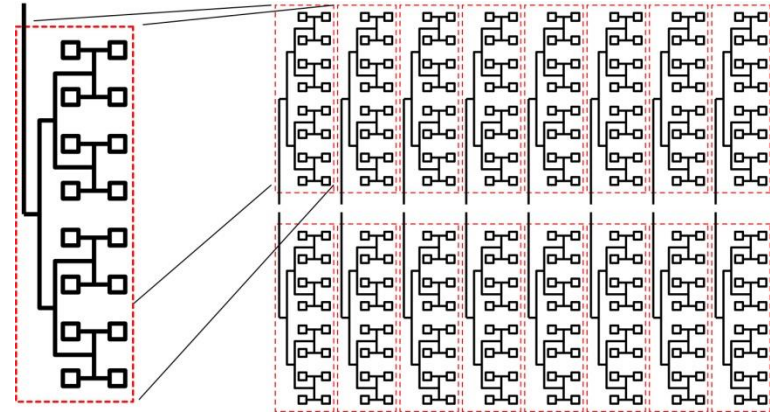
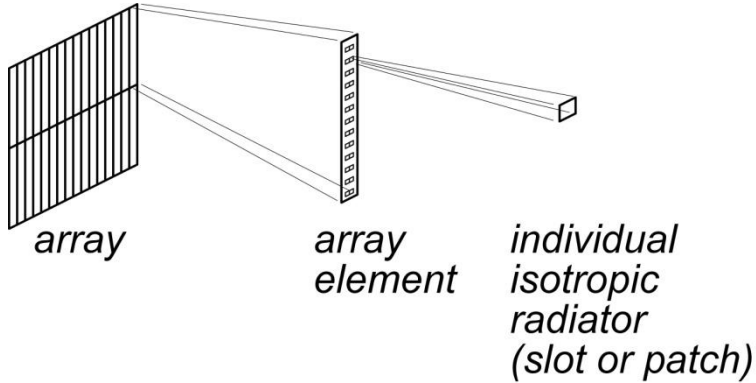
Packaging and antennas

The Antenna Feed Loss Problem

array elements are many λ long
 overall array can be very big
 → **high feed line losses**

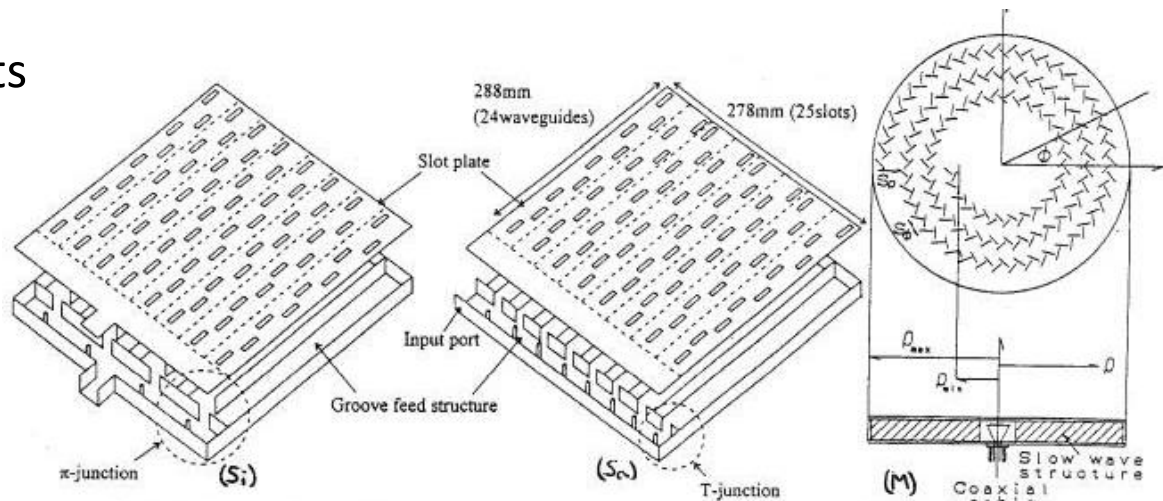


Use distribution amplifiers ?



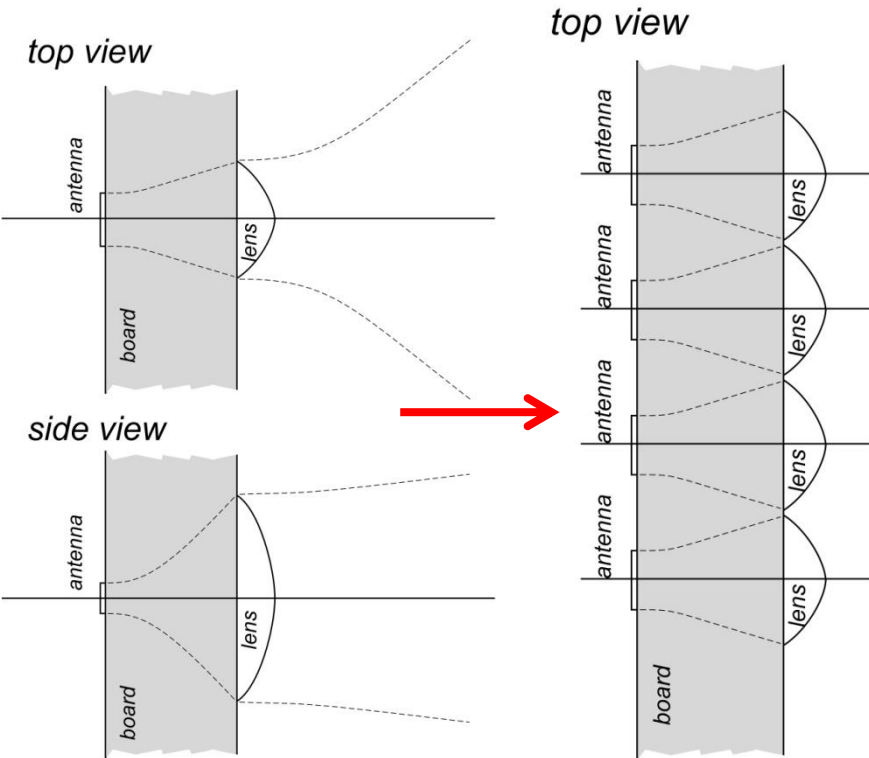
One solution:
 waveguide-fed arrays of slots

Use to feed array tile:
 overall array needs steering

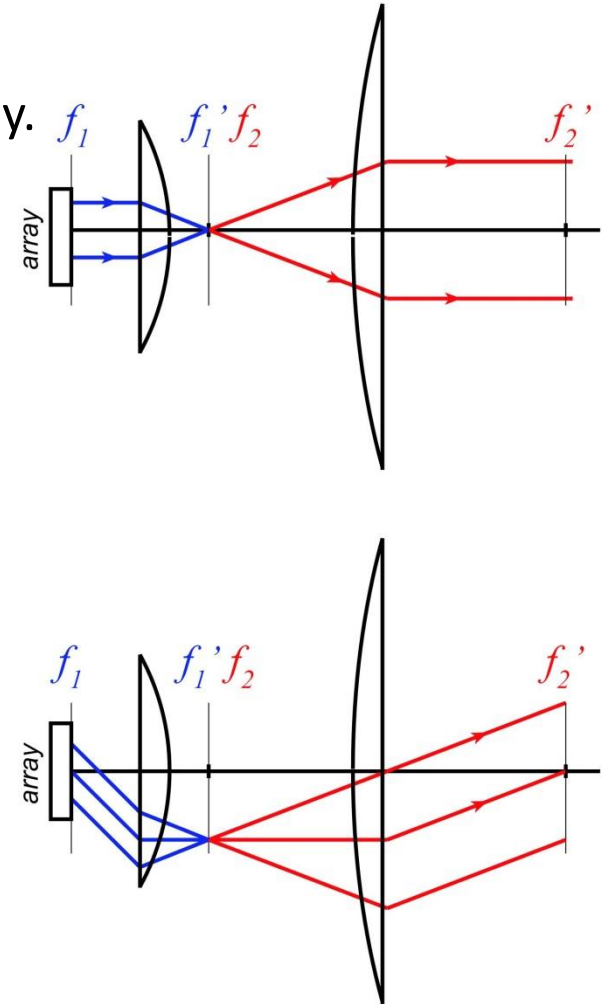


Using lenses to reduce feed loss

Lenses on individual array elements.



...or on the overall array.

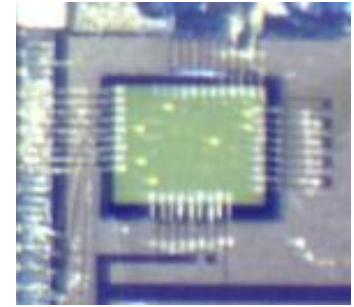


Here the challenge is maintaining constant beamwidth over wide steering angles.

mm-wave interfaces: packaging

Wire-bonds:

With care, >60GHz can be coupled over wire-bonds.
Coupling of multiple lines remains problematic .



Flip-chip bonds

Standard C4 bonds very capacitive; tuning OK @ 60GHz. Possibly higher.
Option: more highly scaled bonds. Must contact vendors.
Heat removal problematic in flip-chip ICs

Flexible polyimide interconnect substrate

Used in Cascade micotech multi-signal probes, in some 60GHz products.
Ground integrity, low inductance mm-wave connections.
Must identify vendor.

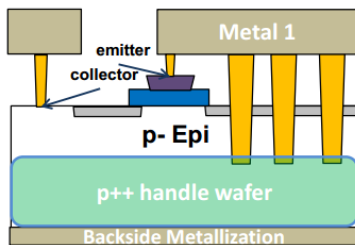


mm-wave interfaces: packaging

Through-silicon vias for RF grounding (TowerJazz, also IBM/GF)
very low ground inductance
low losses, low crosstalk in mm-wave IC-package connections

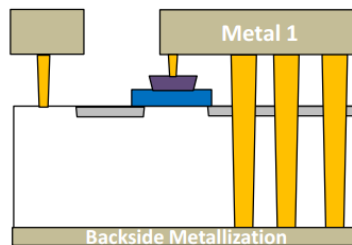
RF Ground Solutions

•Deep Silicon Vias

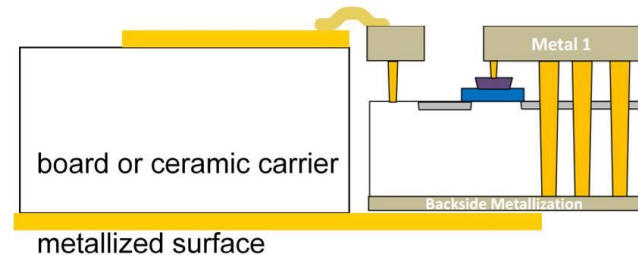


- Extremely “localized” grounding. DSVs can be placed within several μm s of active devices.
- $<5\text{pH}/\text{via}$. $<50\text{ W}/\text{via}$
- In production now

•Through-Silicon Vias



- Through-Silicon Vias for low inductance / low resistance emitter ground leads
- $1000\ \mu\text{m}^2$ Pad can produce 22pH inductance to ground with less than $1\text{W}/\text{via}$
- In prototype now



mm-wave IC Design

Reactively-Tuned IC Design: Concepts

What's the most gain we can get ? Do we care ?

Maximum available gain : unconditionally stable transistor. No feedback. Match.

$$G_{ma} = \left\| \frac{S_{21}}{S_{12}} \right\| \cdot \left(K - \sqrt{K^2 - 1} \right) \quad \text{where } K = \frac{1 - \|S_{11}\|^2 - \|S_{22}\|^2 + \|S_{11}S_{22} - S_{12}S_{21}\|^2}{2 \cdot \|S_{12}S_{21}\|} \text{ (Rollet stability factor).}$$

Maximum stable gain : potentially unstable transistor. No feedback. Stabilize. Match.

$$G_{ms} = \left\| \frac{S_{21}}{S_{12}} \right\|$$

Unilateral gain : lossless feedback until $S_{12} = 0$, then match

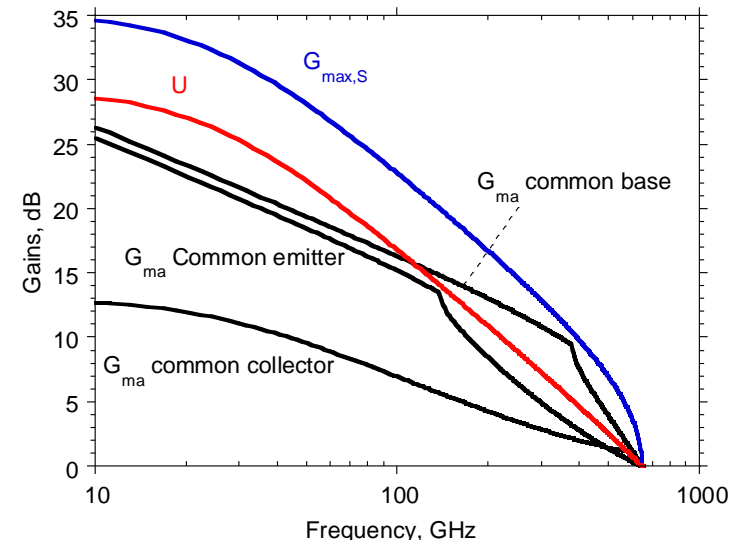
$$U = \frac{|Y_{21} - Y_{12}|^2}{4(G_{11}G_{22} - G_{21}G_{12})}$$

Singhakowinta's gain :

appropriate lossless reactive feedback, match

$$G_{\max,S} = (2U - 1) + 2U^{1/2} (U - 1)^{1/2}$$

Highest feasible gain given unconditional stability



What's the most gain we can get ? Do we care ?

Low-noise amplifiers

designed for low noise figure, fairly high IP3

Power amplifiers

designed for high Psat, PAE, sufficiently low IM3

IF amplifiers

designed for low noise figure, high IP3.

Practical amplifiers are rarely designed for highest gain.

Real-world relevance of G_{ma} , G_{ms} , $G_{max,S}$ is not clear.

Practical designs would benefit from ***new theory***

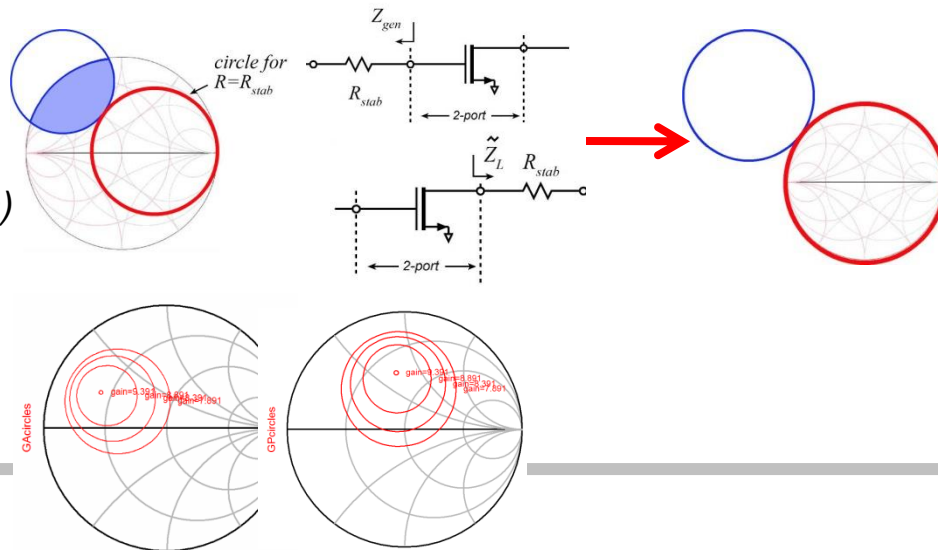
Quantities similar to G_{ma} , G_{ms} , $G_{max,S}$ above

But under constraints of high-power or low-noise tuning.

I know of no such published work.

RF-IC Design: Simple & Well-Known Procedures

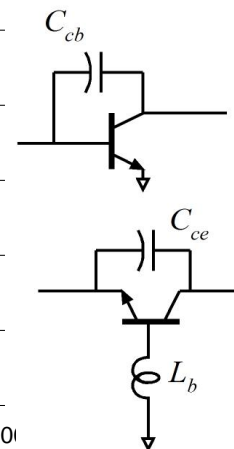
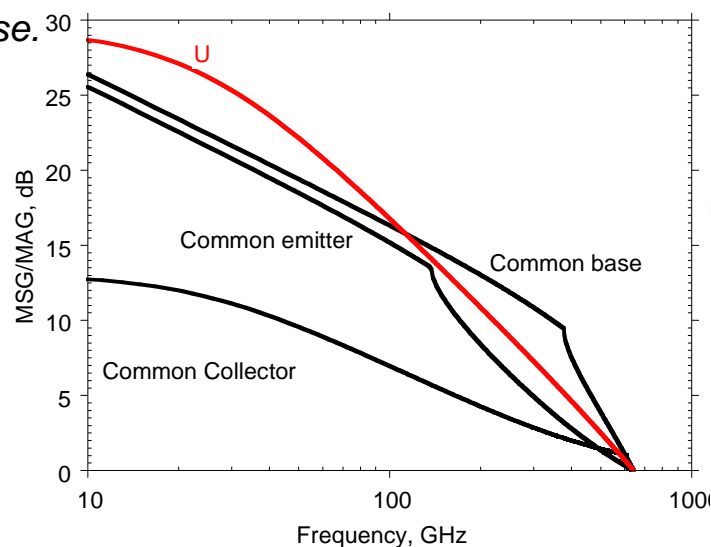
- 1: (over)stabilize at the design frequency guided by stability circles
- 2: Tune input for F_{min} (LNAs) or output for P_{sat} (PAs)
- 3: Tune remaining port for maximum gain
- 4: Add out-of-band stabilization.



There are many ways to tune port impedances: microstrip lines, MIM capacitors, transformers
Choice guided by tuning losses. No particular preferences.

For BJT's, MAG/MSG usually highest for common-base.

Common-base gain is however reduced by:
base (layout) inductance
emitter-collector layout capacitance.

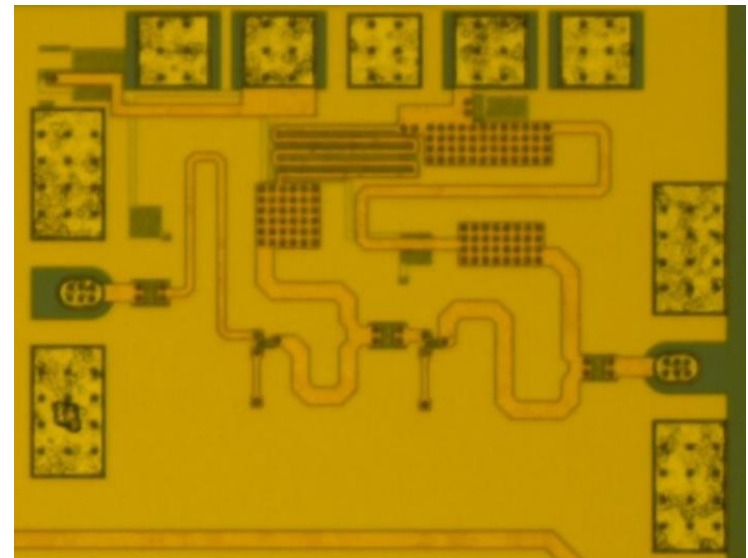
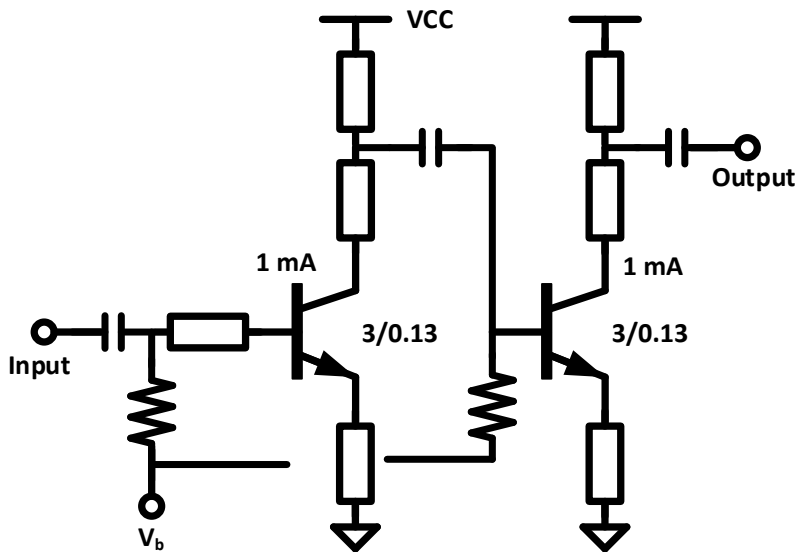
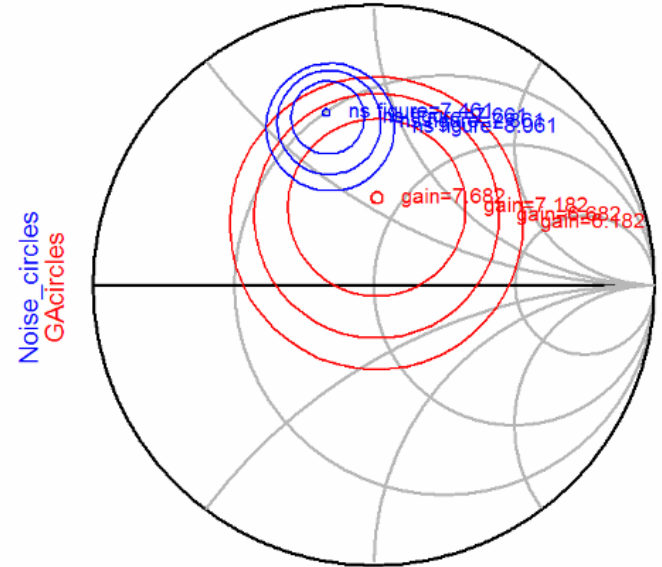


Low-Noise Amplifier Design

Noise and Available Gain Circles

Inductive emitter/source degeneration
 simultaneous S11 and noise match
 reduces gain, improves IP3

Additional in-band stabilization (output port) as needed
 Input tuning for F_{\min}
 Output match
 Out-of-band stabilization

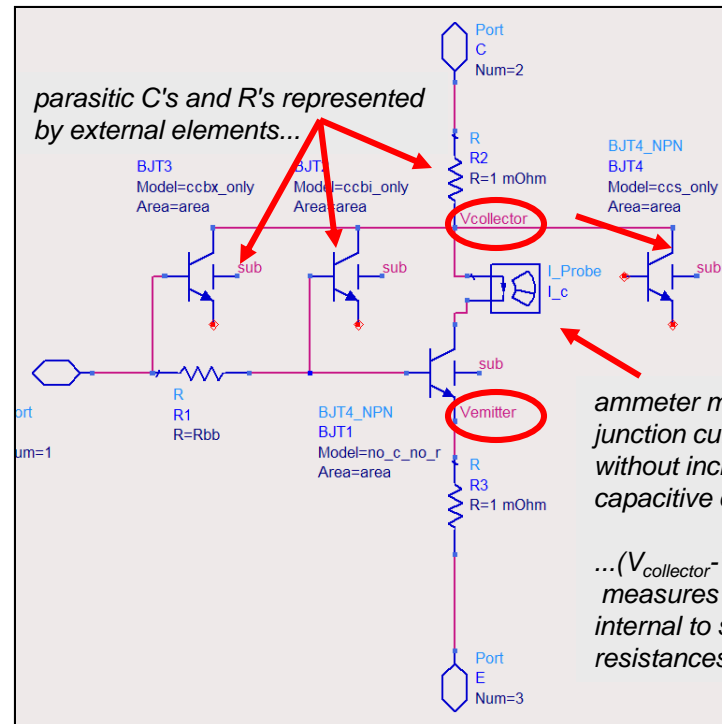
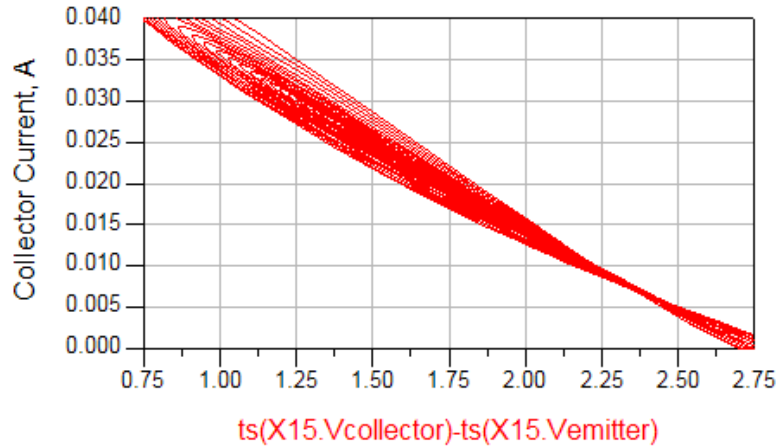
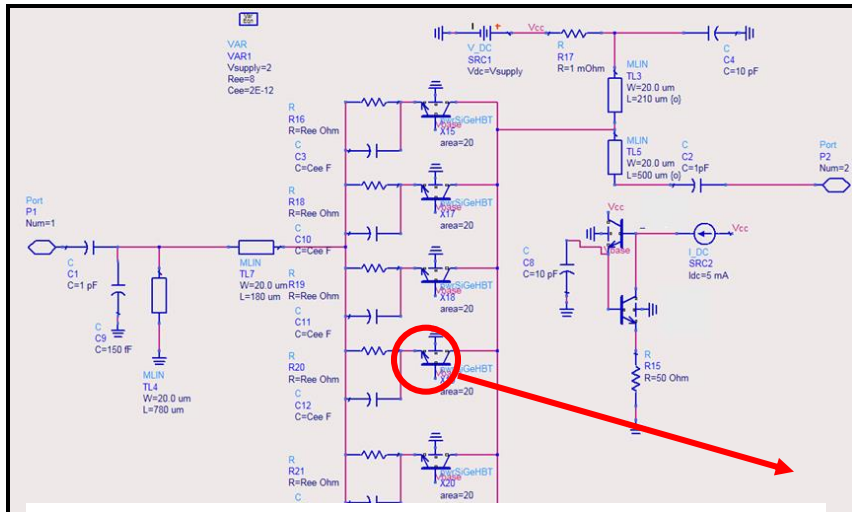
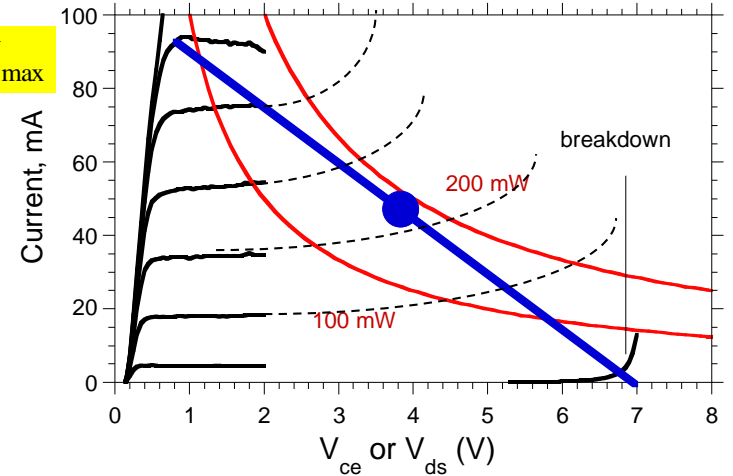


Power Amplifier Design (Cripps method)

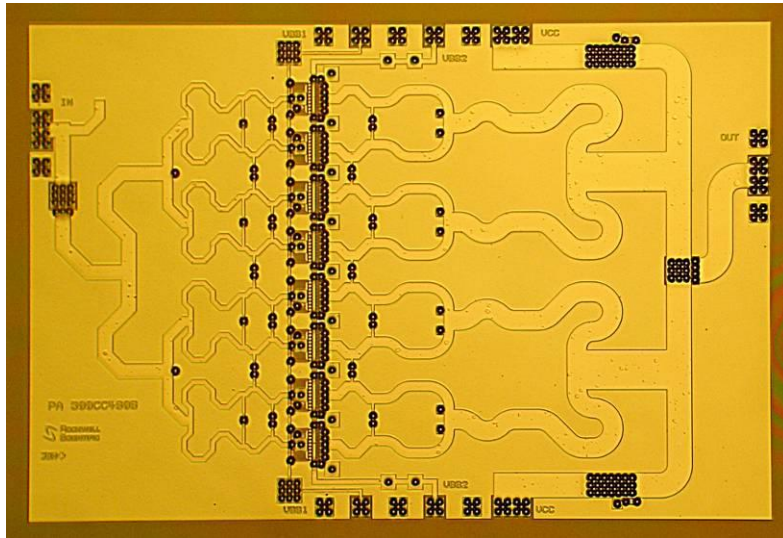
For maximum saturated output power,
& maximum efficiency
device intrinsic output must see
optimum loadline set by:

$$P_{\max} = (1/8)(V_{\max} - V_{\min})I_{\max}$$

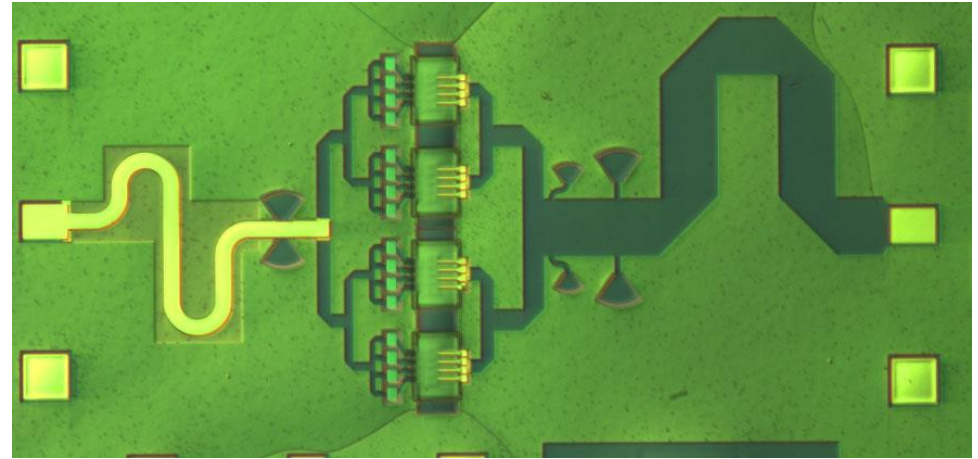
breakdown, maximum current, maximum power density.



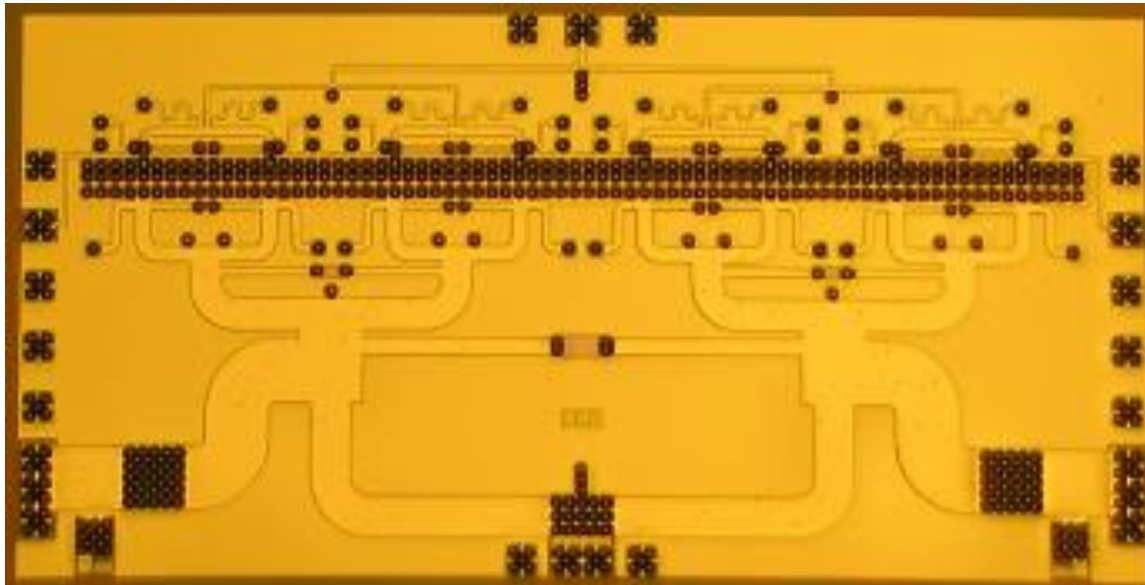
PAs with corporate combining



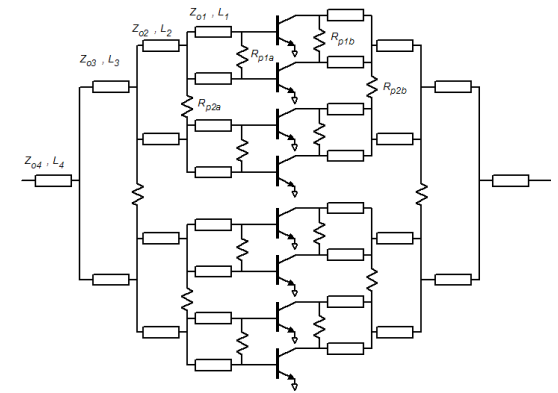
34 GHz InP HBT power amplifier - J. Hacker Teledyne



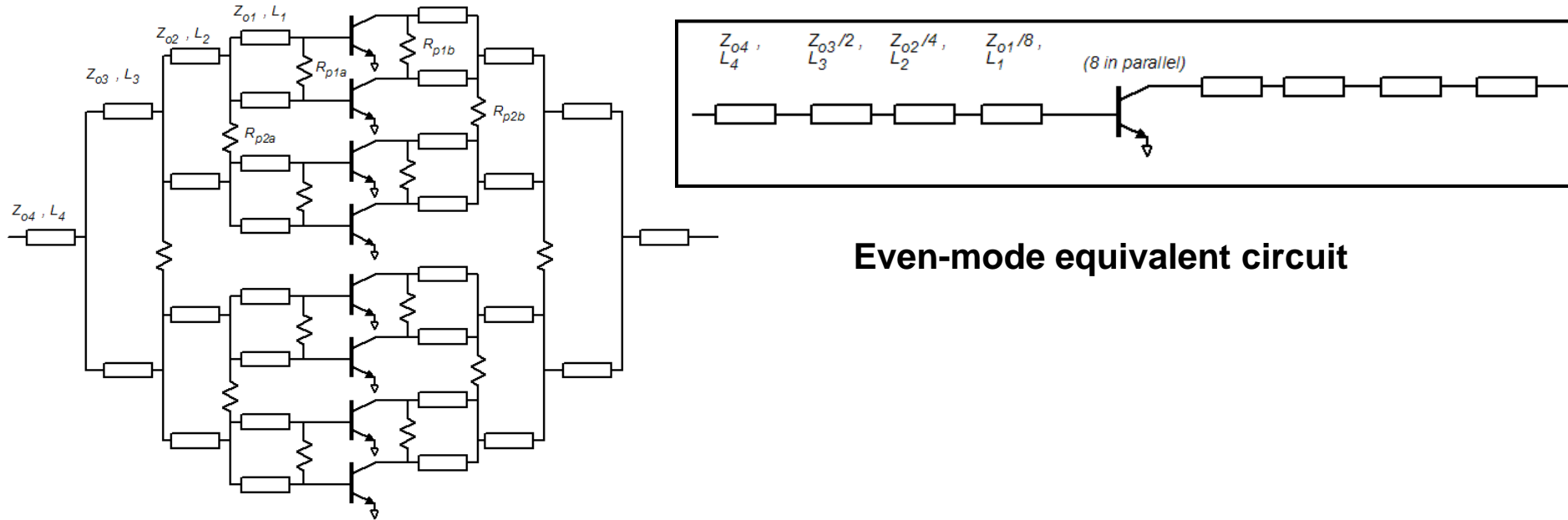
W-band InP HBT power amplifier - UCSB



34 GHz InP HBT power amplifier - J. Hacker Teledyne



Power amplifier design: combiners



Even-mode equivalent circuit

The equivalent circuit : a multi - section transmission - line transformer.

Shunt elements (inductors, capacitors) can also be added.

Line parameters are adjusted to reach $Z_{l,opt}$ and to match input.

CAD approach :

all similar lines defined by shared variables, simultaneously adjusted

mm-wave IC Interconnects

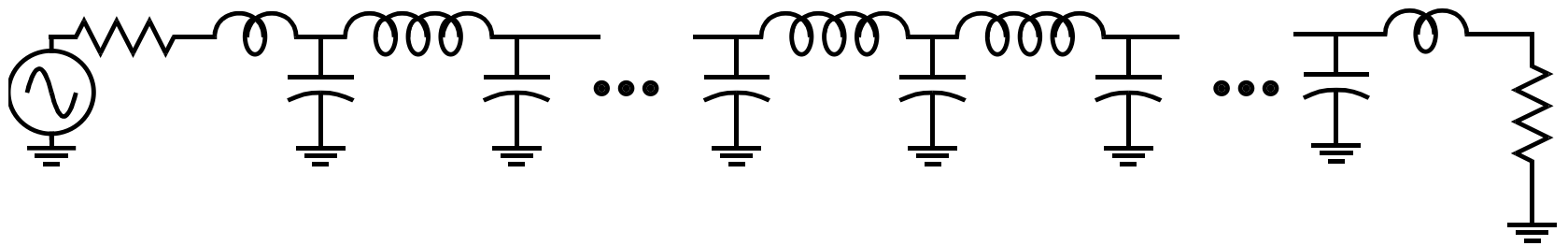
Transmission Lines

A pair of wires with *regular spacing*, *dielectric loading* along the length.

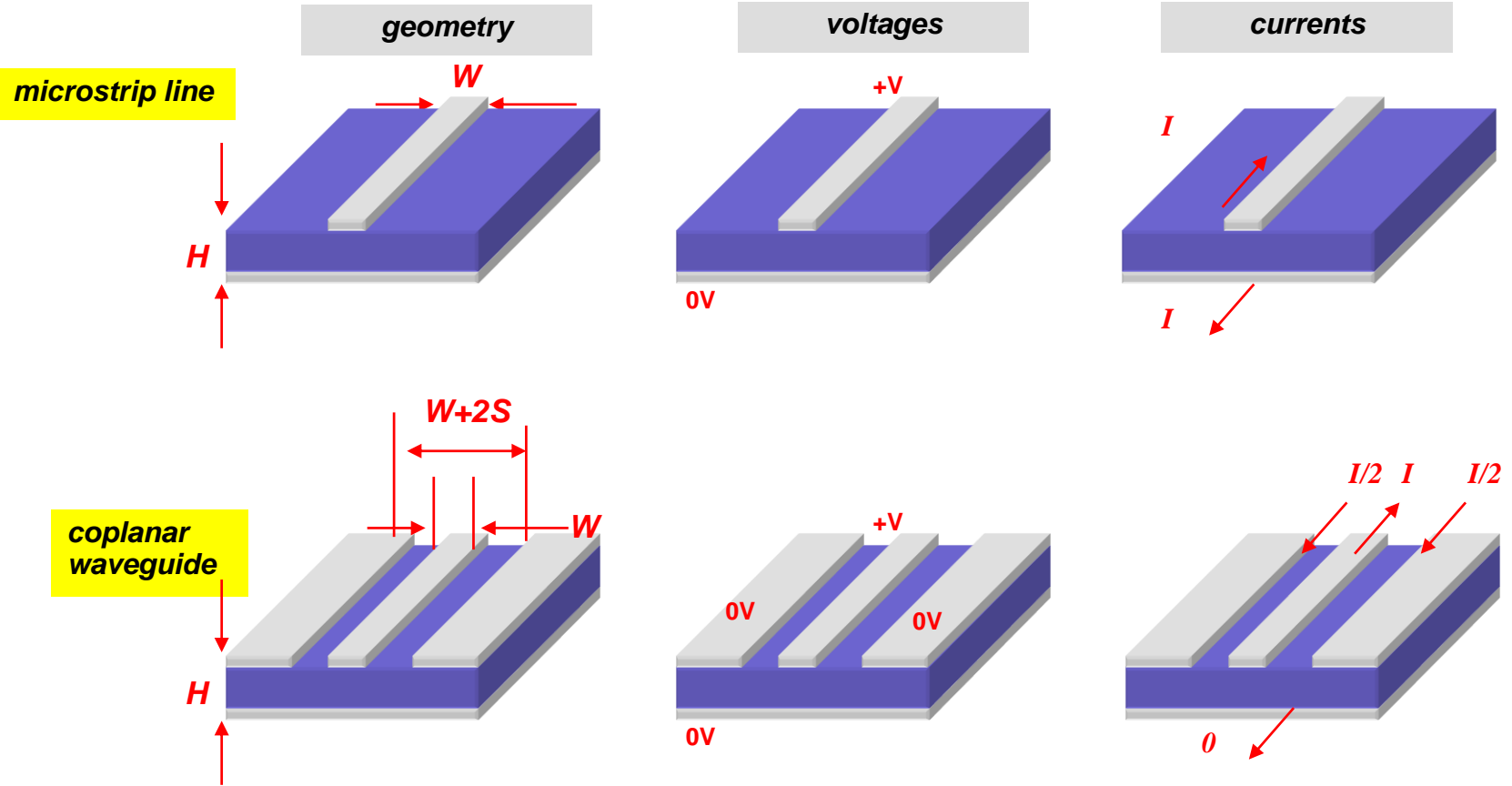
These have inductance per unit length and capacitance per unit length.

Forward and reverse waves propagate.

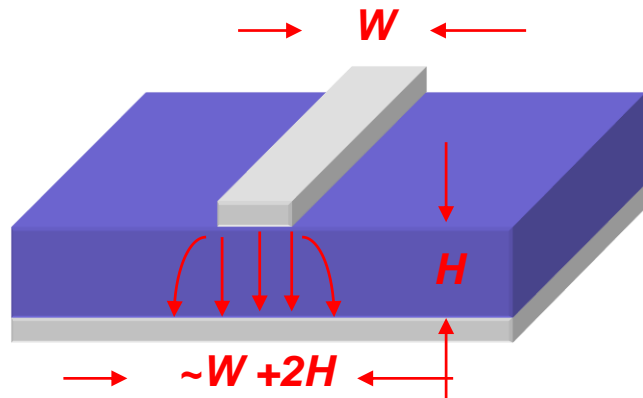
Reflections will occur if lines are not terminated in Z_0



Transmission Lines for On-Wafer Wiring



Skin loss



Skin depth $\delta = \sqrt{2 / \omega \mu \sigma}$:

Gold: $\delta \cong 200 \text{ nm @ } 100 \text{ GHz}$,
 $640 \text{ nm @ } 10 \text{ GHz}$

Series resistance per unit length :

$$R_{series} / L \approx \frac{1}{\delta \sigma} \frac{1}{W} + \frac{1}{\delta \sigma} \frac{1}{W + 2H}$$

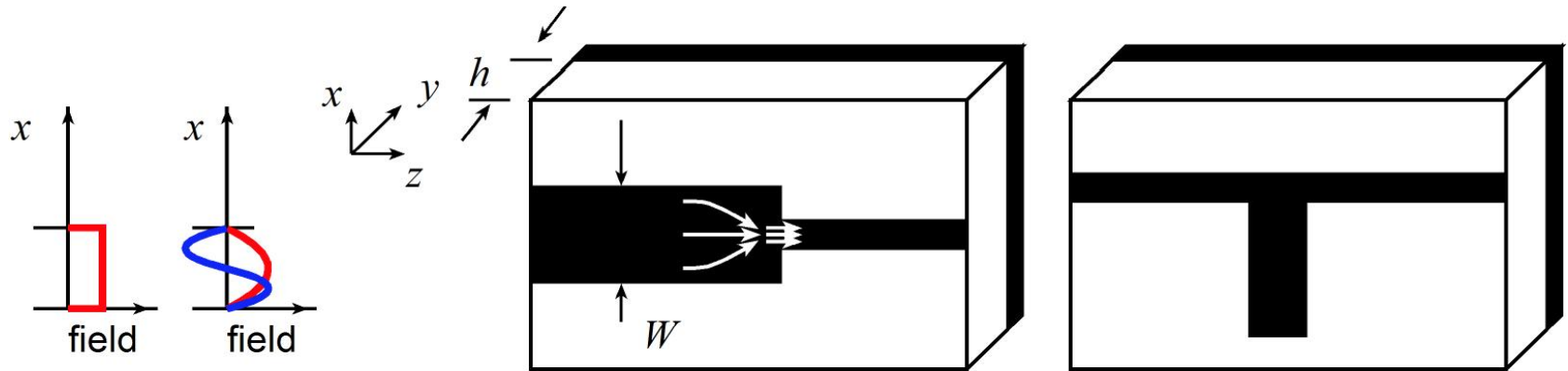
Attenuation per unit distance

$$\alpha \cong \frac{R_{series} / L}{2Z_0} \propto \sqrt{f}$$

Exponential signal decay

$$V(z) = V_o \exp(-\alpha z) \exp(-j2\pi z / \lambda_g)$$

Lateral Modes (1)



In dielectric : waves of form $\vec{E}_0 e^{j\omega t} e^{\pm jk_x x} e^{\pm jk_y y} e^{\pm jk_z z}$

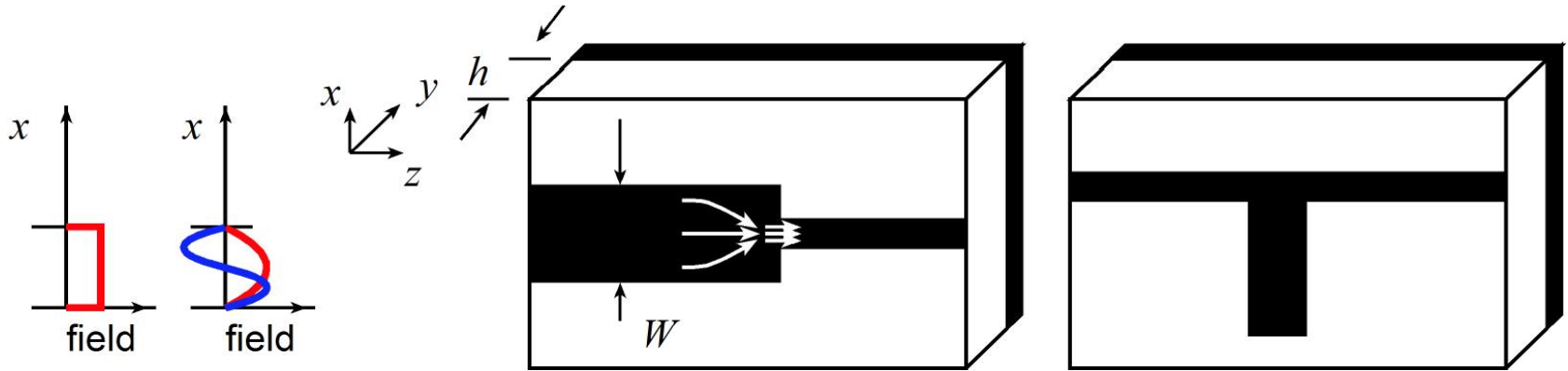
$$k_x^2 + k_y^2 + k_z^2 = k^2 = \epsilon_r \omega^2 / c^2 = (2\pi / \lambda_d)^2$$

Waves can propagate *laterally* on transmission - line :

$$k_y = 0 \text{ and } k_x = n\pi / W \text{ for } n = 0, 1, 2, \dots$$

$$\rightarrow k_z^2 = \epsilon_r \omega^2 / c^2 - (n\pi / W)^2$$

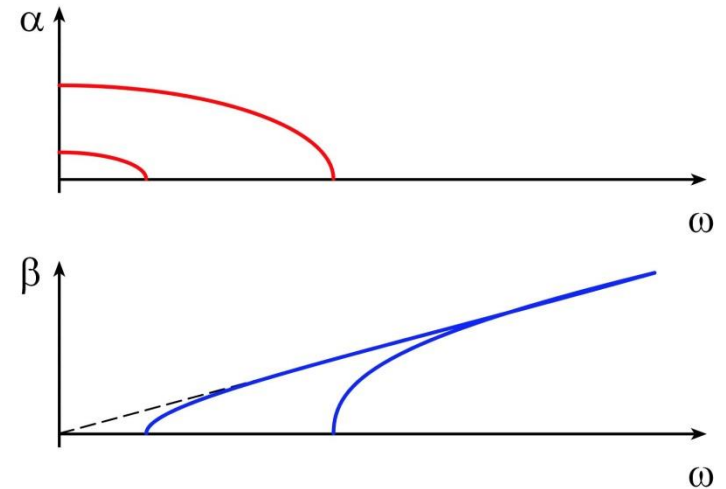
Lateral Modes (2)



$$k_z^2 = \epsilon_r \omega^2 / c^2 - (n\pi / W)^2$$

1) Multi - mode propagation if $W > \lambda_d/2$.

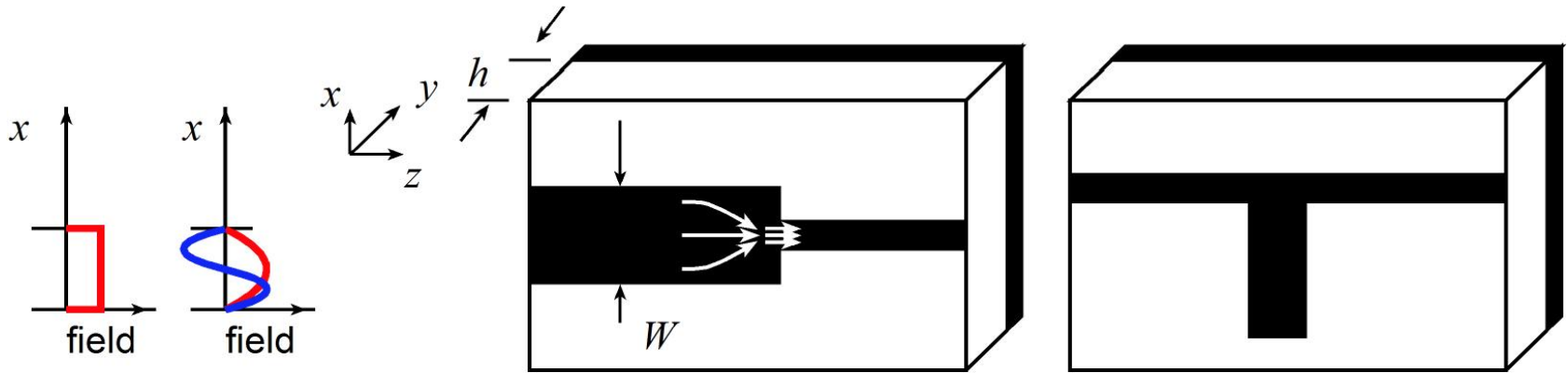
$$\beta_z = \sqrt{\epsilon_r \omega^2 / c^2 - (n\pi / W)^2}$$



2) Evanescent propagation $e^{-\alpha_z z}$ if $W < \lambda_d/2$:

$$\alpha_z = \sqrt{(n\pi / W)^2 - \epsilon_r \omega^2 / c^2}$$

Lateral Modes (3) → Junction Parasitics



Evanescent propagation $e^{-\alpha_z z}$ if $W \cong \lambda_d/2$:

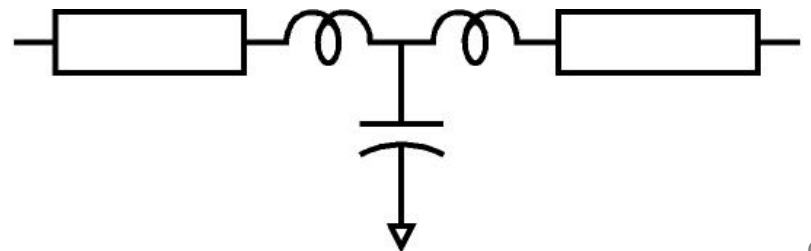
Reactive power in evanescent modes → junction parasitics

ADS library junction models, or electromagnetic simulation.

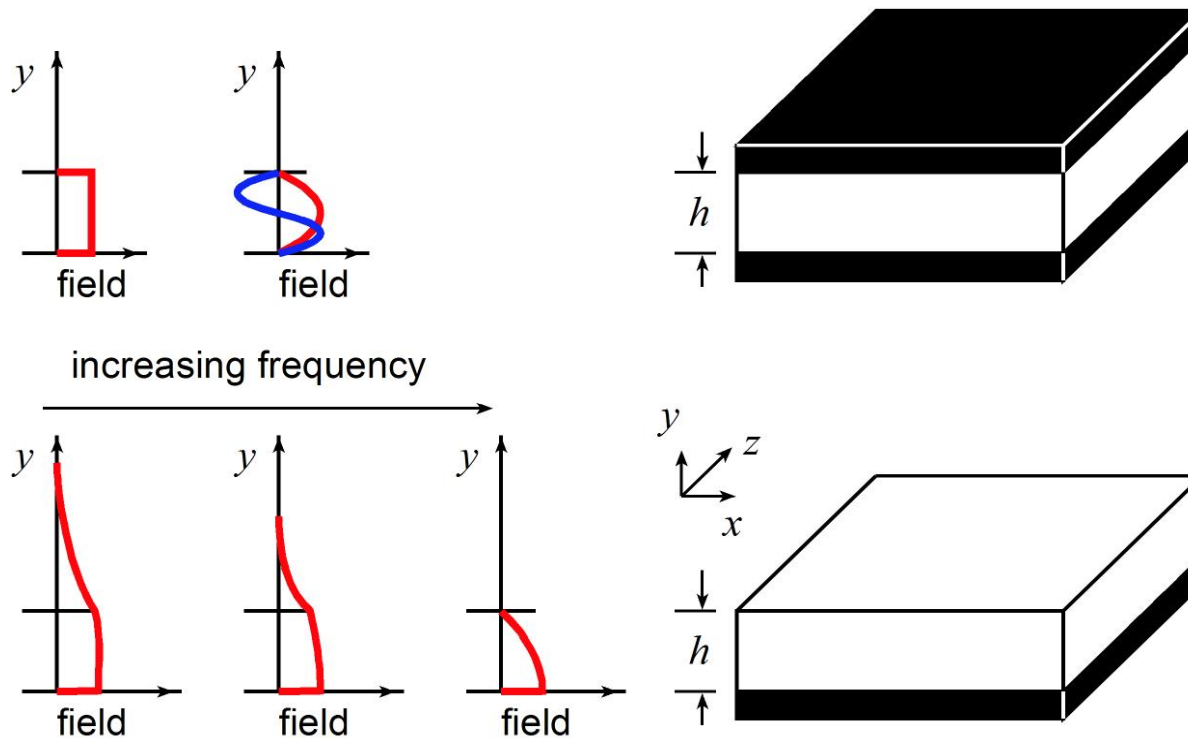
Lessons :

lines must be much narrower than a half-wavelength.

must model junction parasitics



Substrate Modes



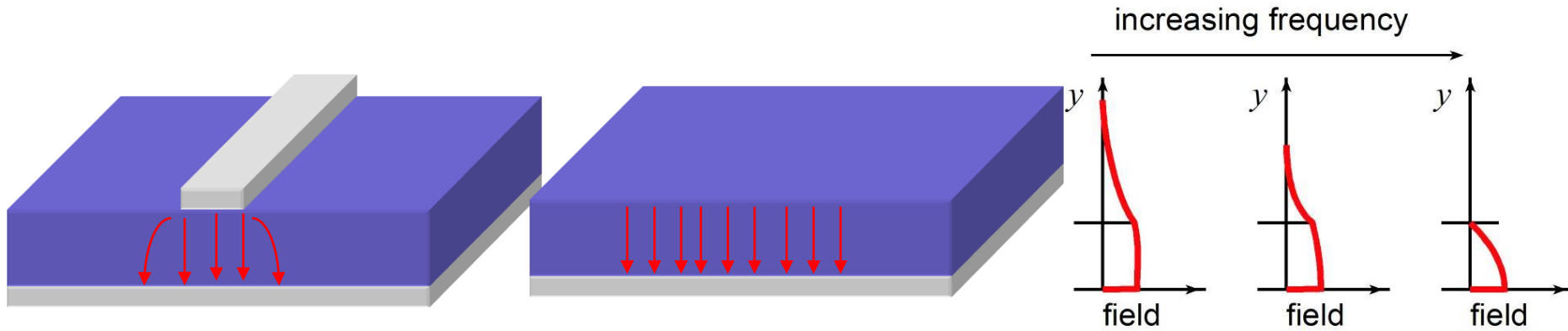
Substrate with top, bottom metal surfaces

→ modes with $h = \lambda_d/2, \lambda_d, 3\lambda_d/2 \dots$

Substrate with no top metal → transverse E - mode;

strongly confined as $\lambda_d/4 \rightarrow T$; weakly confined at low frequencies.

Substrate Mode Coupling: Microstrip

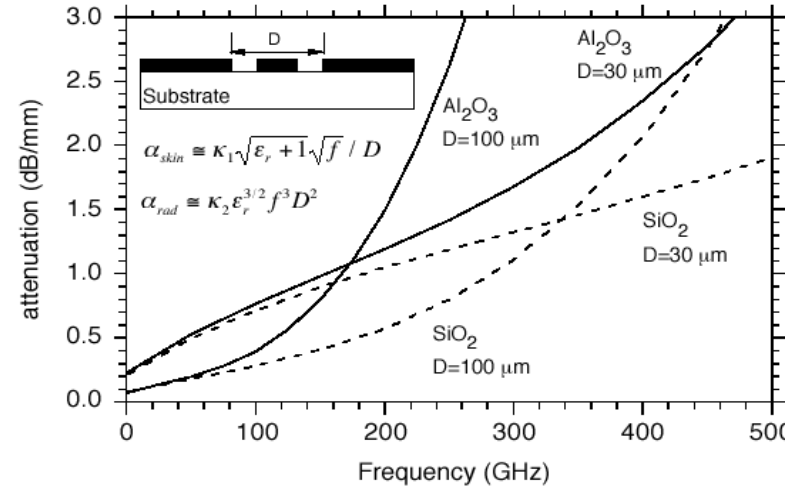
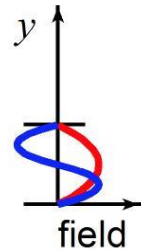
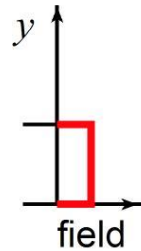
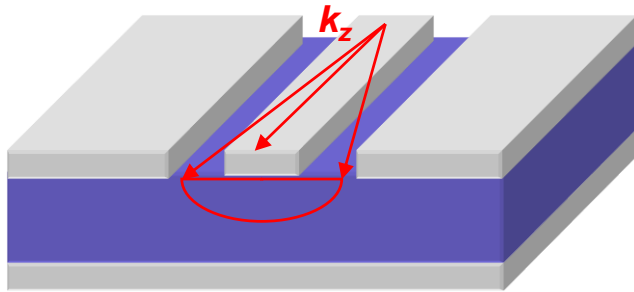


These dielectric slab modes can propagate in x and in z .

Nonzero mode coupling ("radiation") loss at all frequencies.

Very strong mode coupling when $h \geq \lambda_d/4$

Substrate Mode Coupling: CPW



Modes couple strongly when $k_{y,CPW} = k_{y,substrate\ mode}$

Given thick substrate, $H \gg \lambda_d$:

mode coupling loss, dB/mm \propto (line transverse dimensions)² · frequency²

"radiation loss"

Transmission lines: the problem

If we use narrow lines and thin substrates
then skin - effect losses will be large.

If we use wide lines and thick substrates
then lateral modes and substrate radiation
will be major problems.

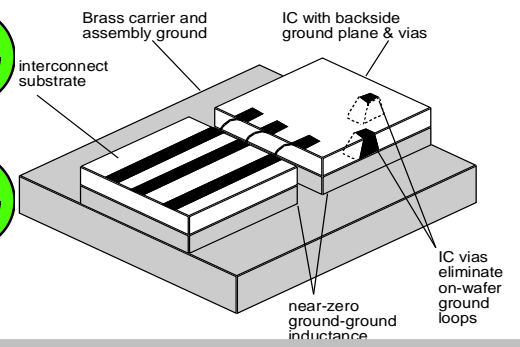
III-V MIMIC Interconnects -- Classic Substrate Microstrip

Thick Substrate
→ low skin loss

$\alpha_{skin} \propto \frac{1}{\epsilon_r^{1/2} H}$

Zero ground inductance in package

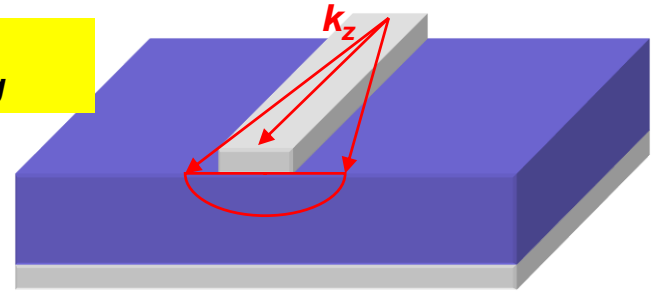
No ground plane breaks in IC



High via inductance

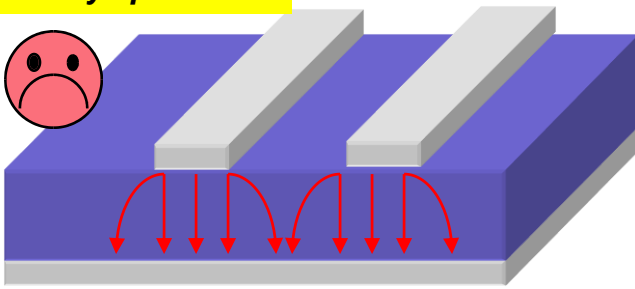
12 pH for 100 μm substrate -- 7.5 Ω @ 100 GHz

TM substrate mode coupling



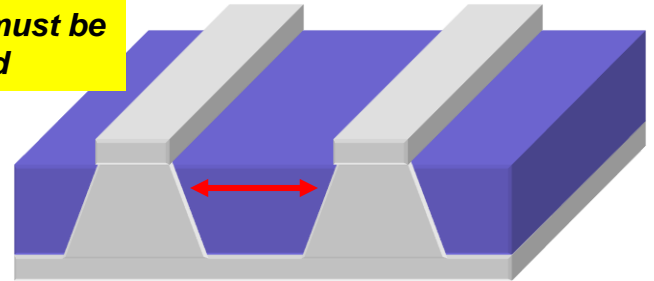
Strong coupling when substrate approaches $\sim \lambda_d / 4$ thickness

lines must be widely spaced



Line spacings must be $\sim 3 \times$ (substrate thickness)

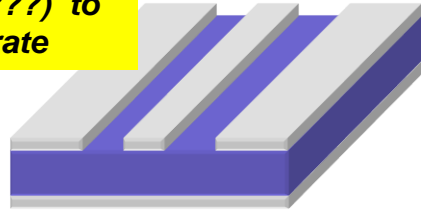
ground vias must be widely spaced



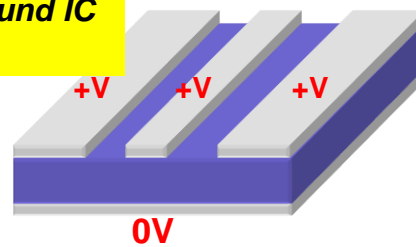
all factors require very thin substrates for >100 GHz ICs
→ lapping to $\sim 50 \mu\text{m}$ substrate thickness typical for 100+ GHz

Coplanar Waveguide

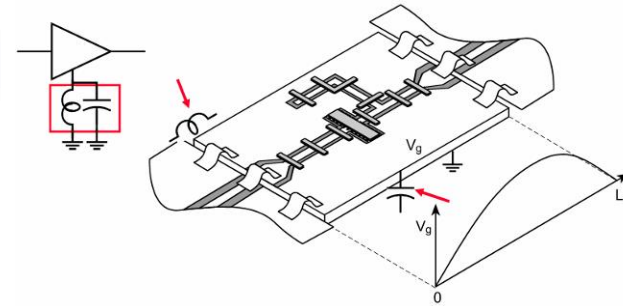
No ground vias
No need (???) to
thin substrate



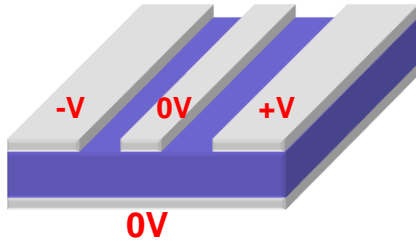
Hard to ground IC
to package



Parasitic microstrip mode

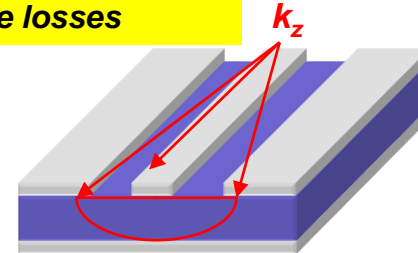


ground plane breaks → loss of ground integrity



Parasitic slot mode

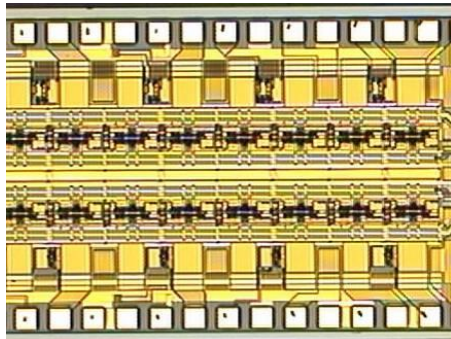
substrate mode coupling
or substrate losses



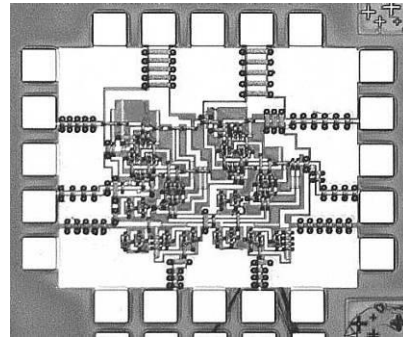
III-V:
semi-insulating
substrate → substrate
mode coupling

Silicon
conducting substrate
→ substrate
conductivity losses

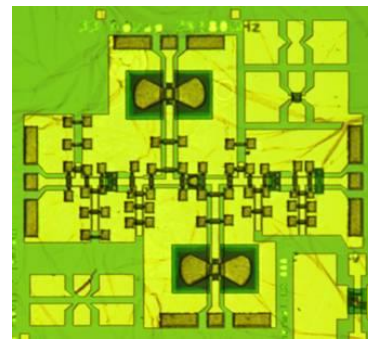
Repairing ground plane with ground straps is effective only in simple ICs
In more complex CPW ICs, ground plane rapidly vanishes
→ common-lead inductance → strong circuit-circuit coupling



40 Gb/s differential TWA modulator driver
note CPW lines, fragmented ground plane



35 GHz master-slave latch in CPW
note fragmented ground plane



175 GHz tuned amplifier in CPW
note fragmented ground plane

poor ground integrity



loss of impedance control



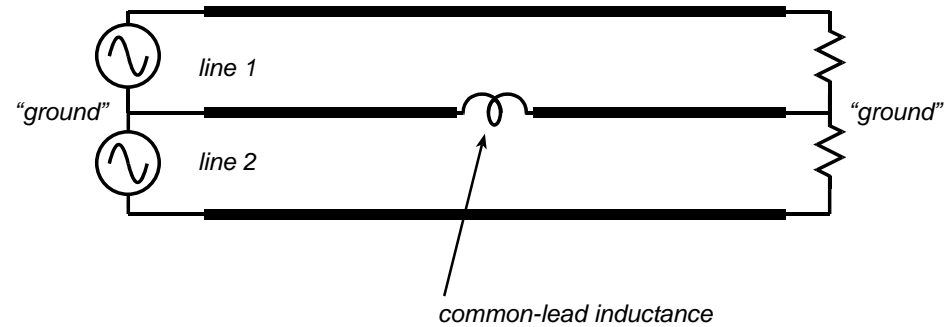
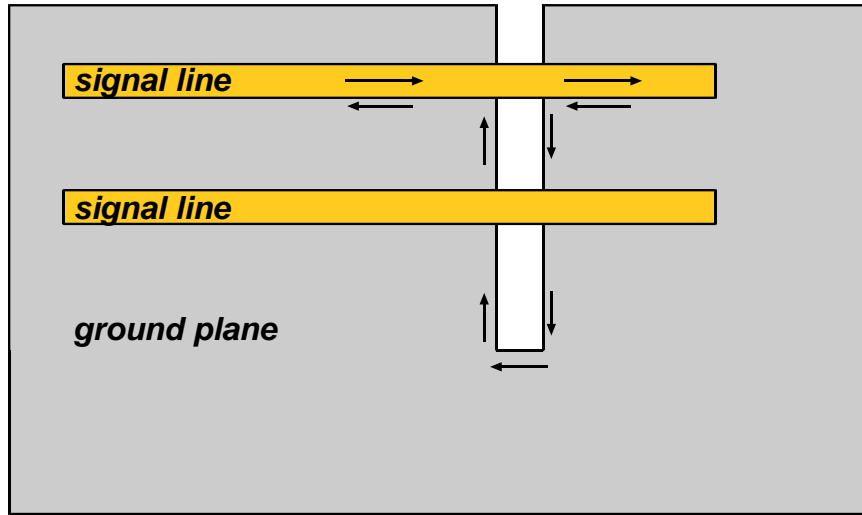
ground bounce



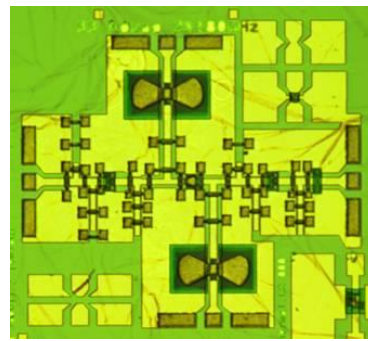
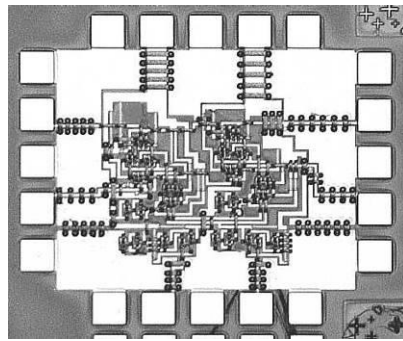
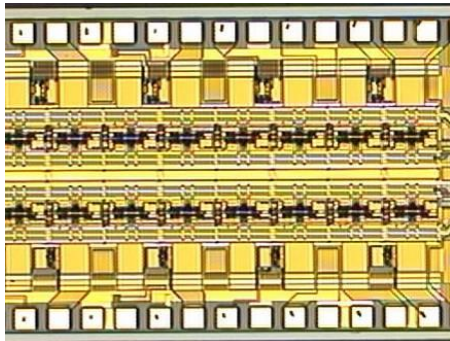
coupling, EMI, oscillation



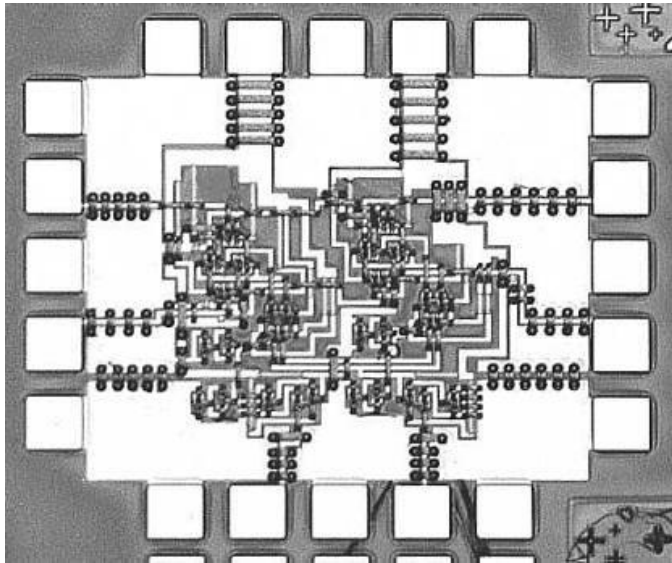
If It Has Breaks, It Is Not A Ground Plane !



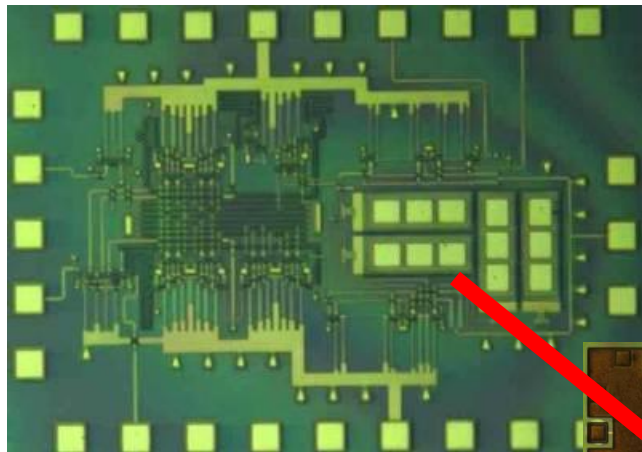
coupling / EMI due to poor ground system integrity is common in high-frequency systems whether on PC boards ...or on ICs.



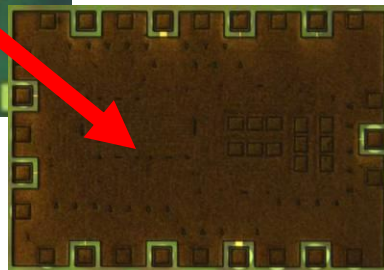
No clean ground return ? → interconnects hard to model



35 GHz static divider
interconnects have no clear local ground return
interconnect inductance is non-local
interconnect inductance has no compact model



8 GHz clock-rate delta-sigma ADC
thin-film microstrip wiring
every interconnect can be modeled as microstrip
some interconnects are terminated in their Z_0
some interconnects are not terminated
...but ALL are precisely modeled



III-V MIMIC Interconnects -- Thin-Film Microstrip

narrow line spacing → IC density



no substrate radiation, no substrate losses



fewer breaks in ground plane than CPW



... but ground breaks at device placements

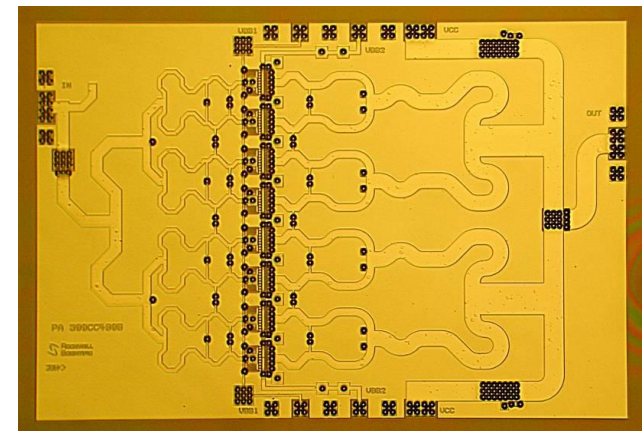
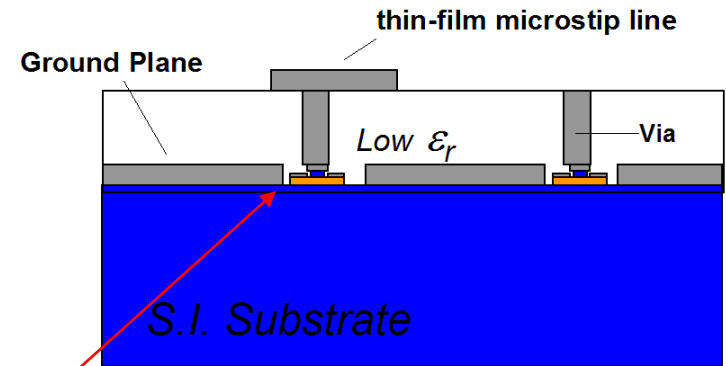


still have problem with package grounding



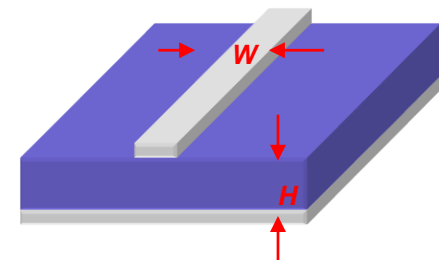
...need to flip-chip bond

thin dielectrics → narrow lines
 → high line losses
 → low current capability
 → no high- Z_o lines



InP 34 GHz PA
 (Jon Hacker, Teledyne)

$$Z_o \sim \frac{\eta_o}{\epsilon_r^{1/2}} \left(\frac{H}{W + H} \right)$$



III-V MIMIC Interconnects -- Inverted Thin-Film Microstrip

narrow line spacing → IC density



Some substrate radiation / substrate losses



No breaks in ground plane



... no ground breaks at device placements

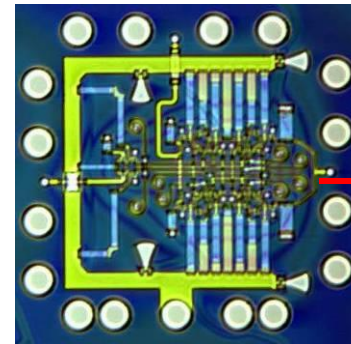
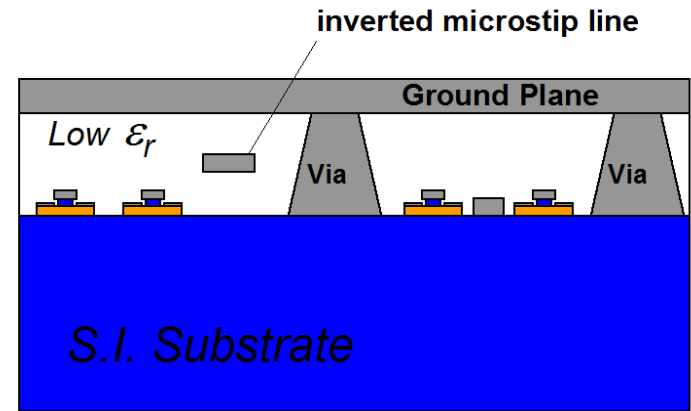


still have problem with package grounding

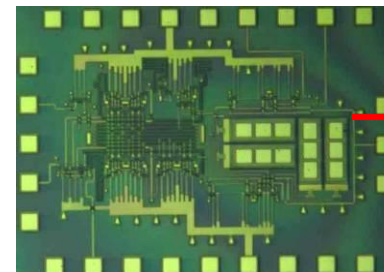
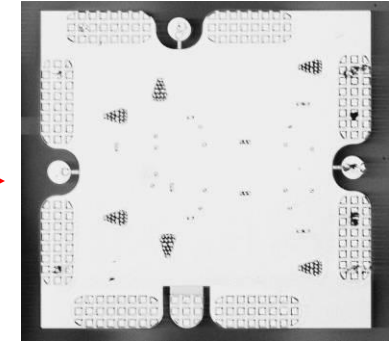


...need to flip-chip bond

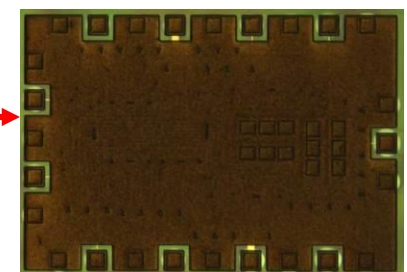
thin dielectrics → narrow lines
→ high line losses
→ low current capability
→ no high- Z_0 lines



InP 150 GHz master-slave latch



InP 8 GHz clock rate delta-sigma ADC



VLSI mm-wave interconnects with ground integrity

narrow line spacing → IC density



no substrate radiation, no substrate losses



negligible breaks in ground plane



negligible ground breaks @ device placements

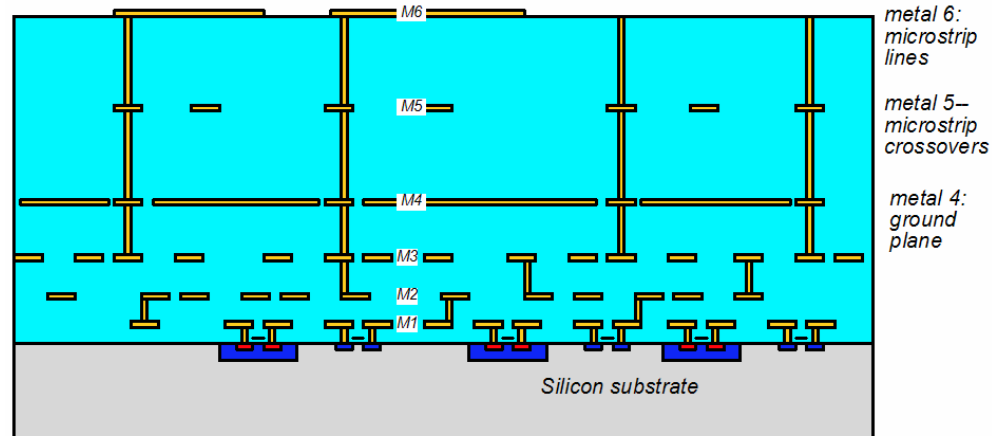


still have problem with package grounding



...need to flip-chip bond

thin dielectrics → narrow lines
→ high line losses
→ low current capability
→ no high- Z_0 lines



Also:

Ground plane at *intermediate level* permits critical signal paths to cross supply lines, or other interconnects without coupling.

(critical signal line is placed above ground, other lines and supplies are placed below ground)

Modeling Interconnects, Passives in Tuned IC's

Interconnects are tuning elements

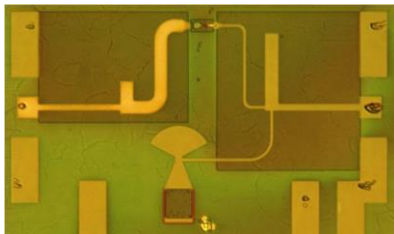
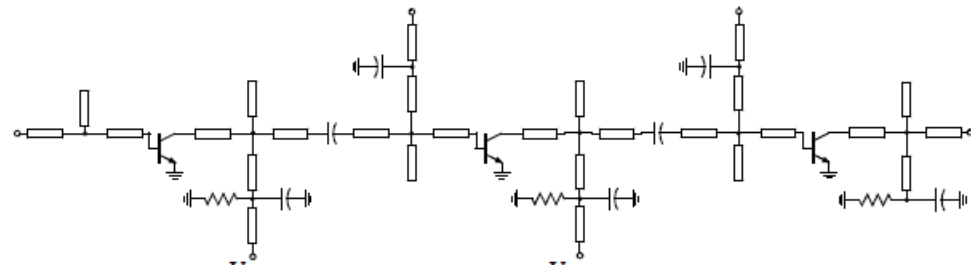
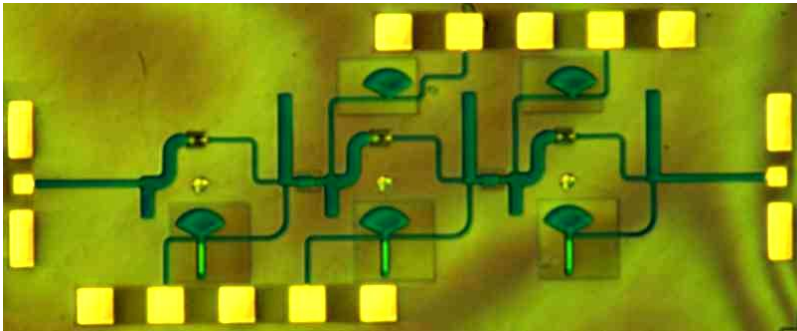
Narrow bandwidths → precision is critical

Initial IC simulation uses CAD-systems' library of passive element models.

*Second design cycle: 2.5-Dimensional electromagnetic simulation of:
lines, junctions, stubs, capacitors, resistors, pads.*

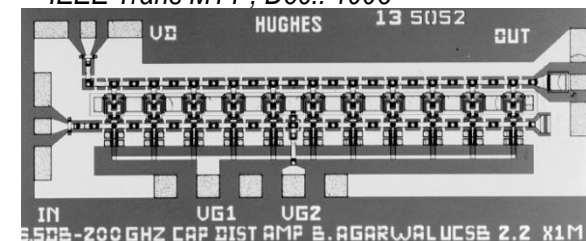
*Third design cycle: 2.5-D simulation of entire IC wiring (if possible);
otherwise, of large blocks (gain stages)*

150-200 GHz HBT amplifier, Urteaga et al, IEEE JSSCC, Sept. 2003

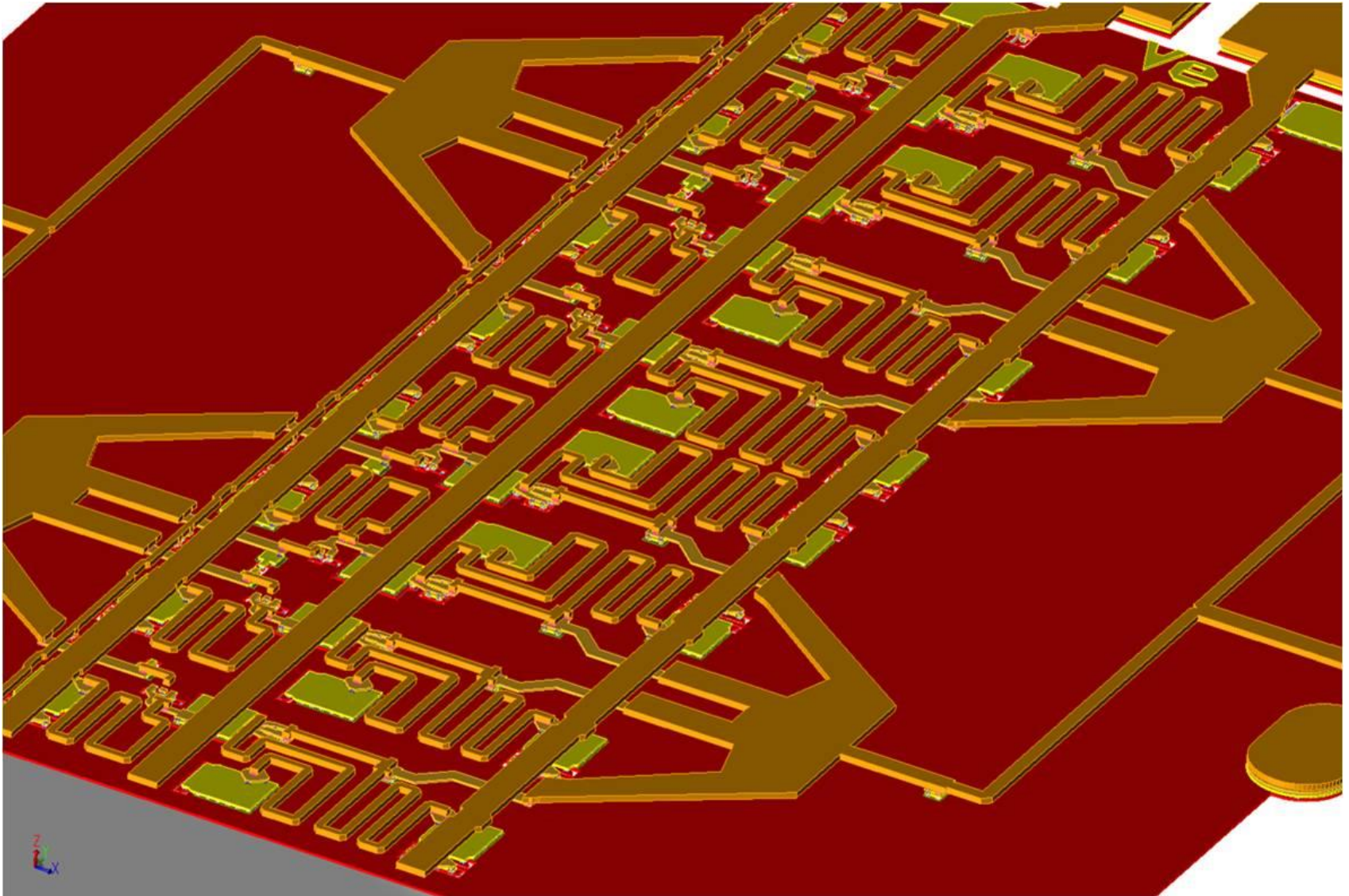


185GHz HBT amplifier, Urteaga et al, IEEE IMS, May. 2001

1-180GHz HBT amplifier, Agarwal et al, IEEE Trans MTT, Dec.. 1998

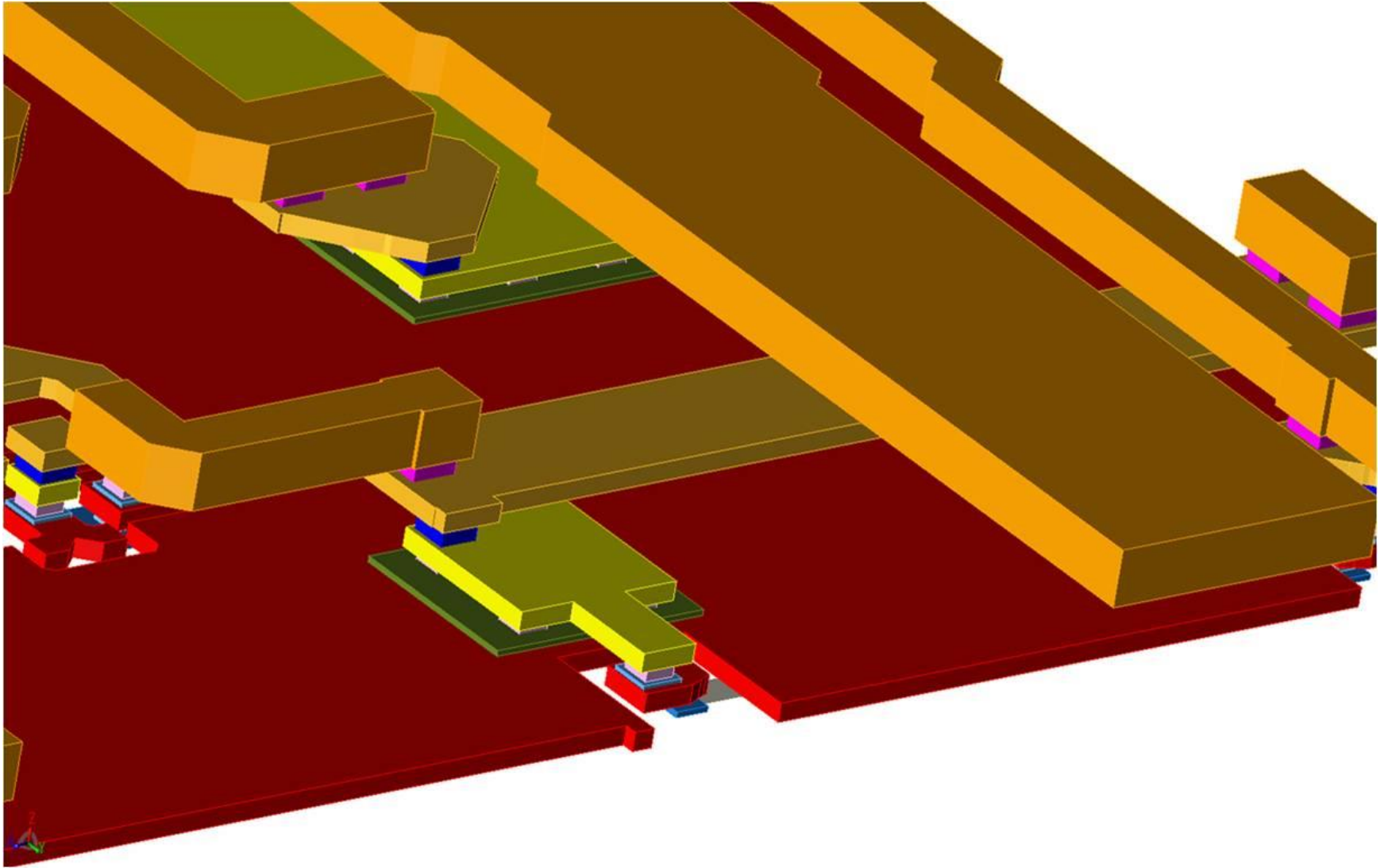


ICs in Thin-Film (Not Inverted) Microstrip



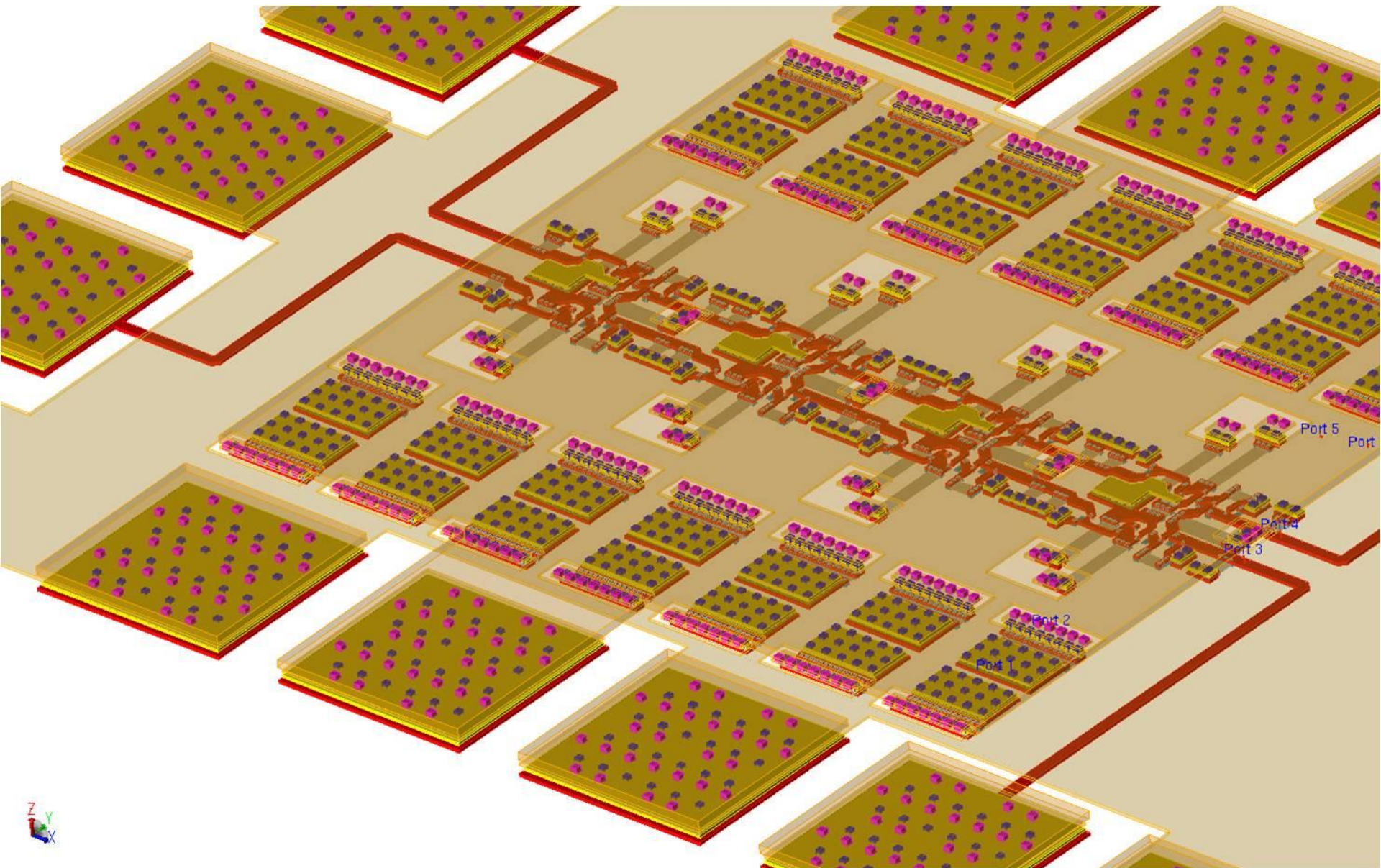
Note breaks in ground plane at transistors, resistors, capacitors

ICs in Thin-Film (Not Inverted) Microstrip



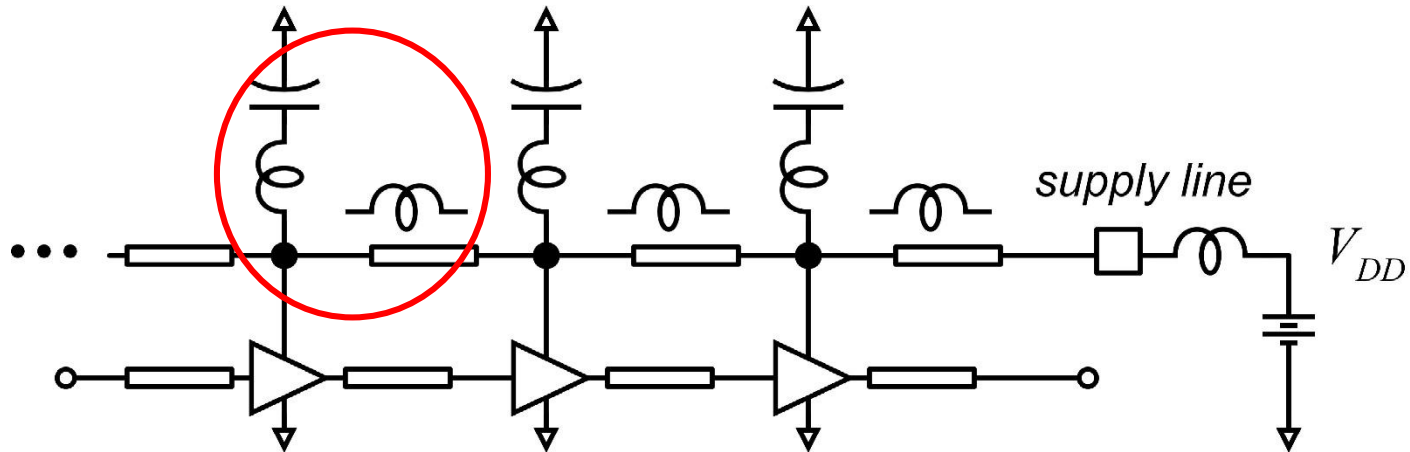
Note breaks in ground plane at transistors, resistors, capacitors

ICs in Thin-Film Inverted Microstrip

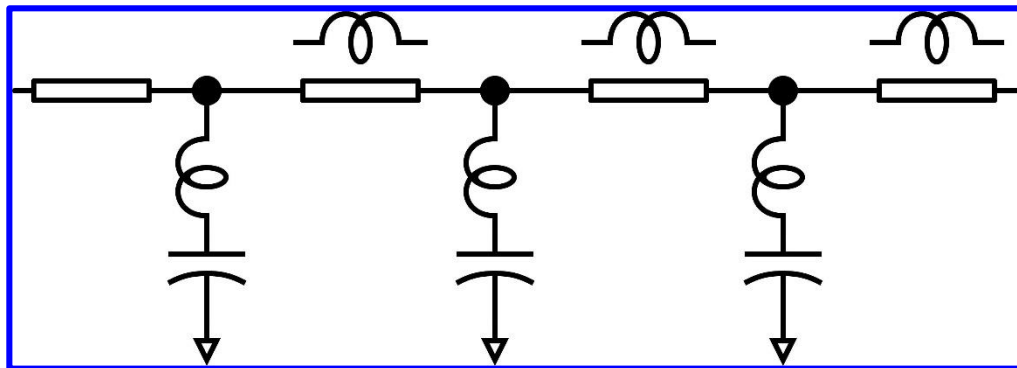


100 GHz differential TASTIS Amp. 512nm InP HBT

Power supply problems



local resonances between bypass cap and supply interconnects
global LC standing-wave resonances on supply bus

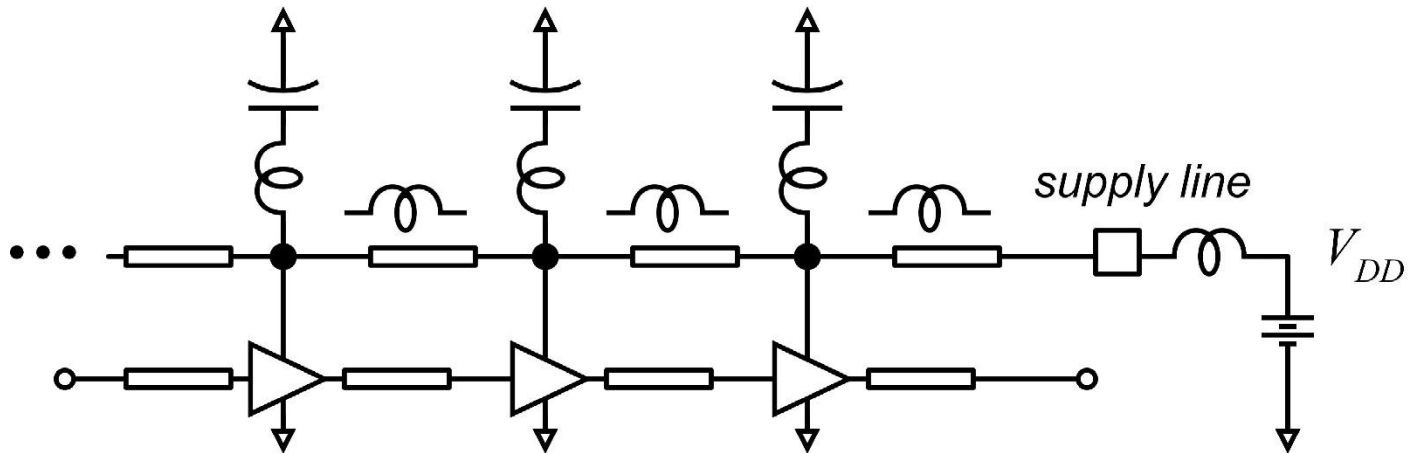
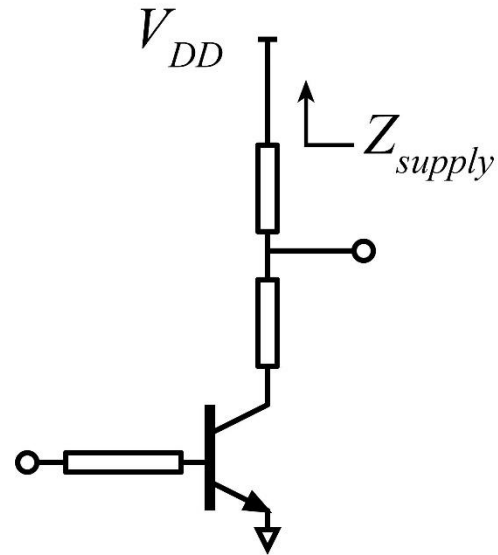


Detuning of individual stages

Coupling, feedback via supply → oscillation, loss of path isolation

Power supply problems

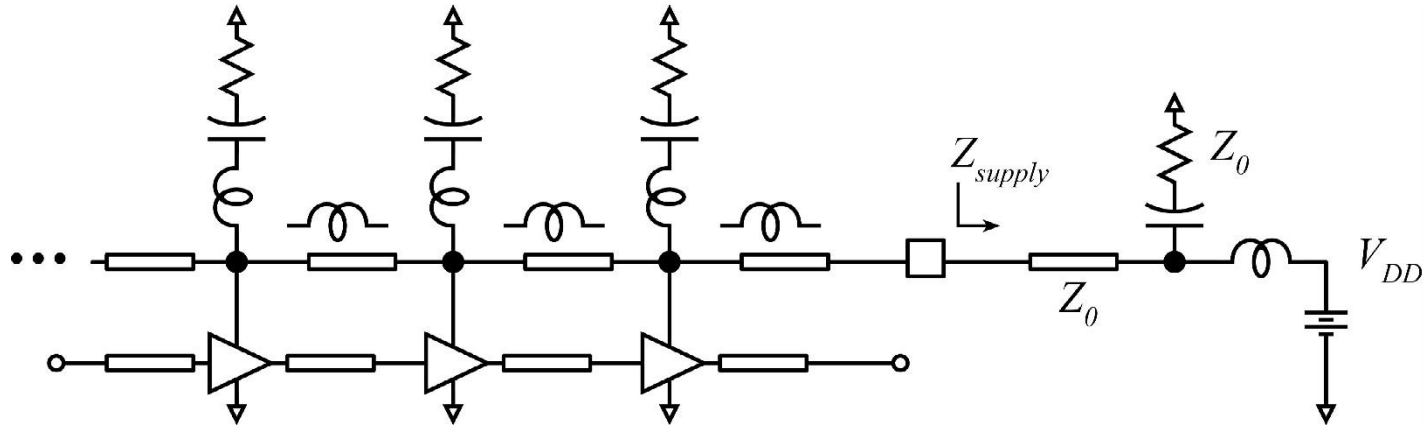
The supply impedance will detune individual stages.



Power supply problems

Model the supply in all simulations.

"If it is on the {IC, PCB, probe station}, put it in the simulation."

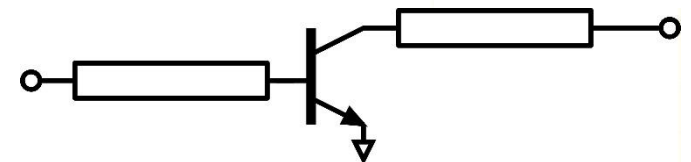
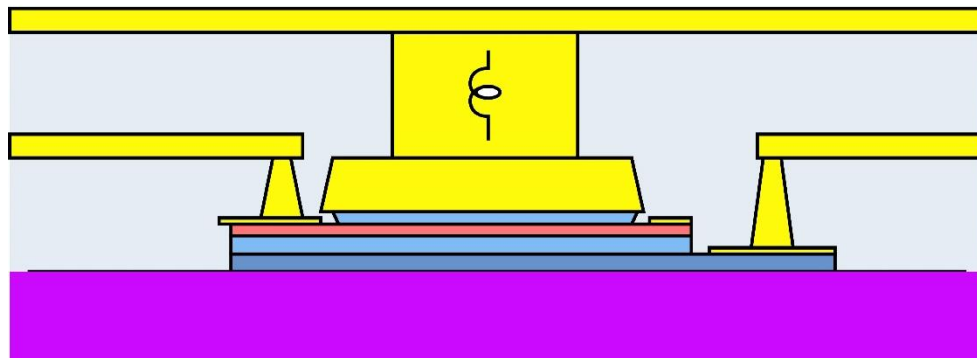
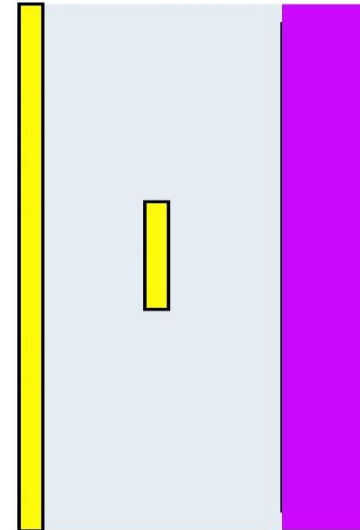
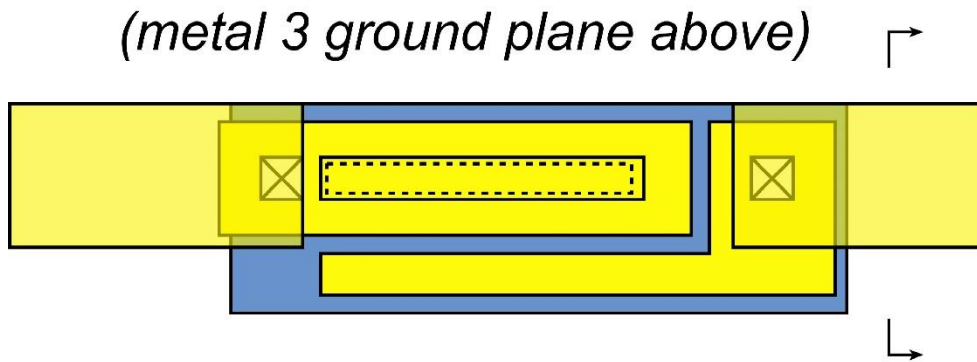


Here, the supply is terminated by 50 Ohms through a bias T. This avoids resonances.

More generally, we must simulate system for wide range of external supply impedance.

Transmission-lines in 500+ GHz ICs

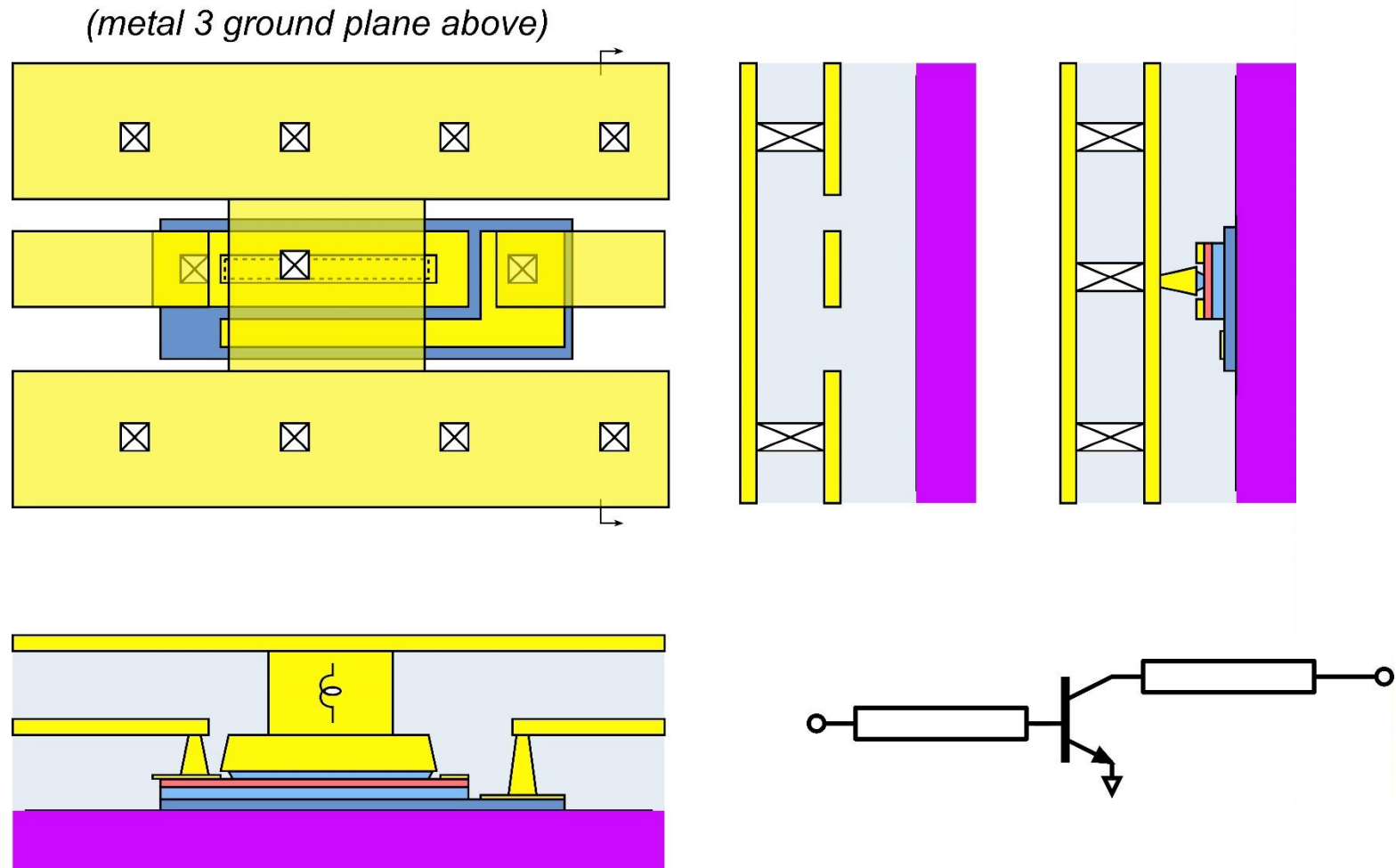
Inverted microstrip: the problem is ground via inductance



Transmission-lines in 500+ GHz ICs

Grounded CPW: lower ground inductance,
metal 3 ground plane suppresses ground bounce

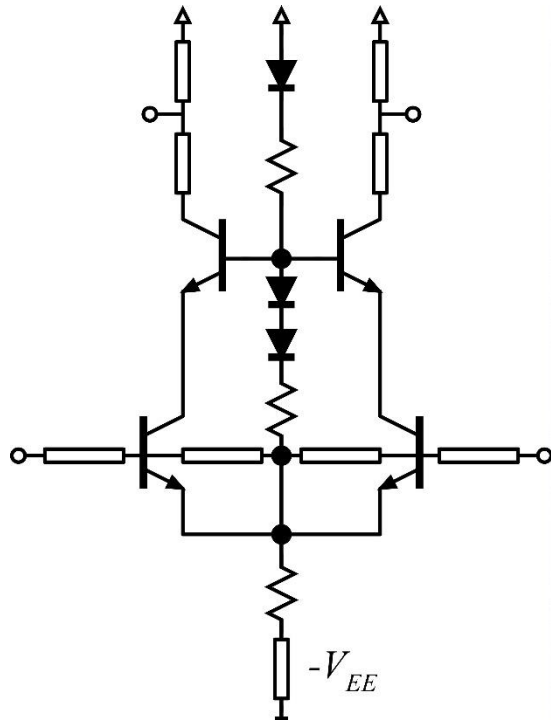
J. Hacker , Teledyne IMS 2013



Differential mm-wave stages

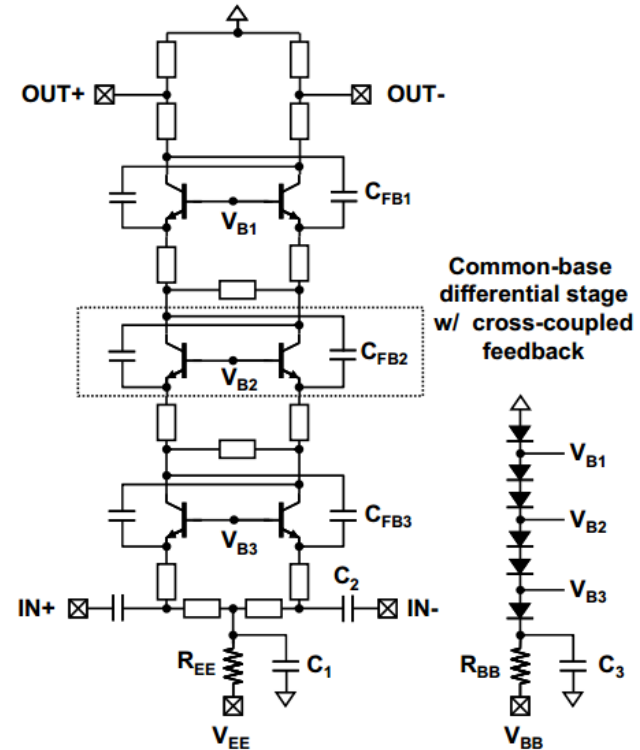
Common-emitter

M. Seo, Teledyne



Common-base

M. Seo, 2013 IMS

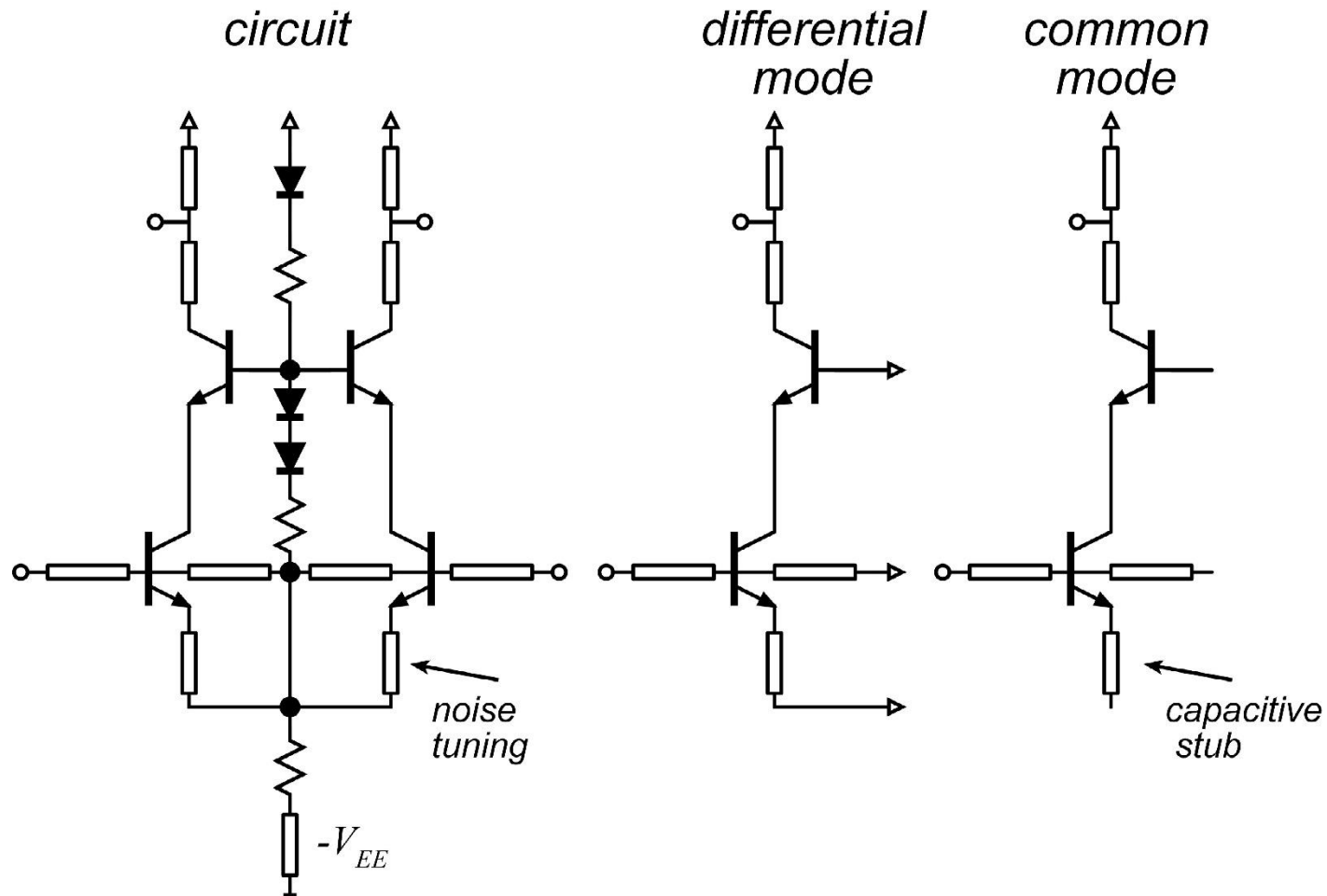


Virtual ground \rightarrow avoids ground via inductance \checkmark

Avoids power-supply coupling \checkmark

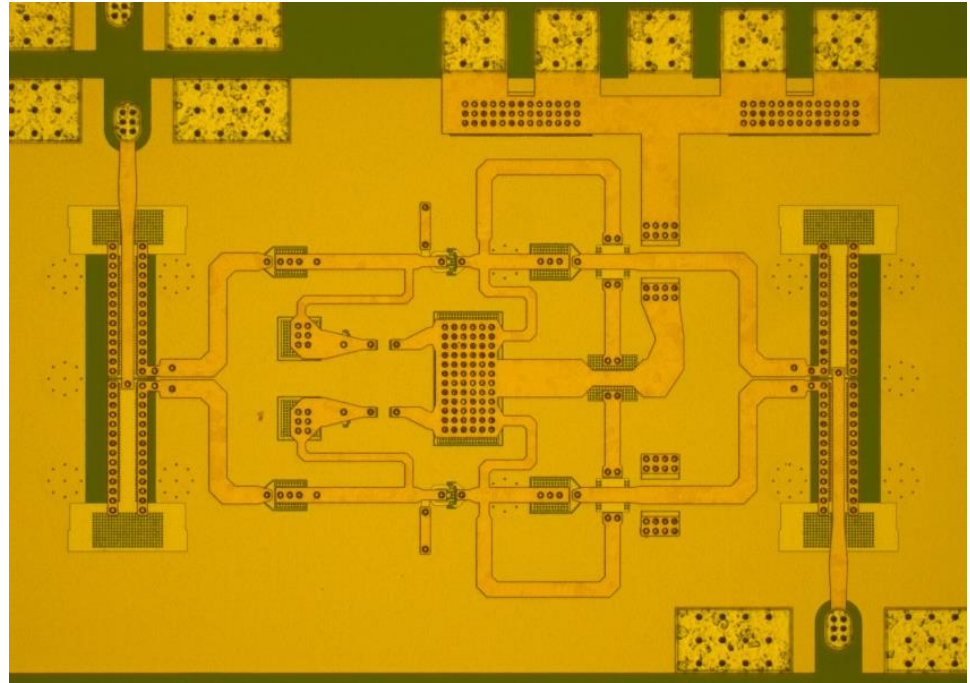
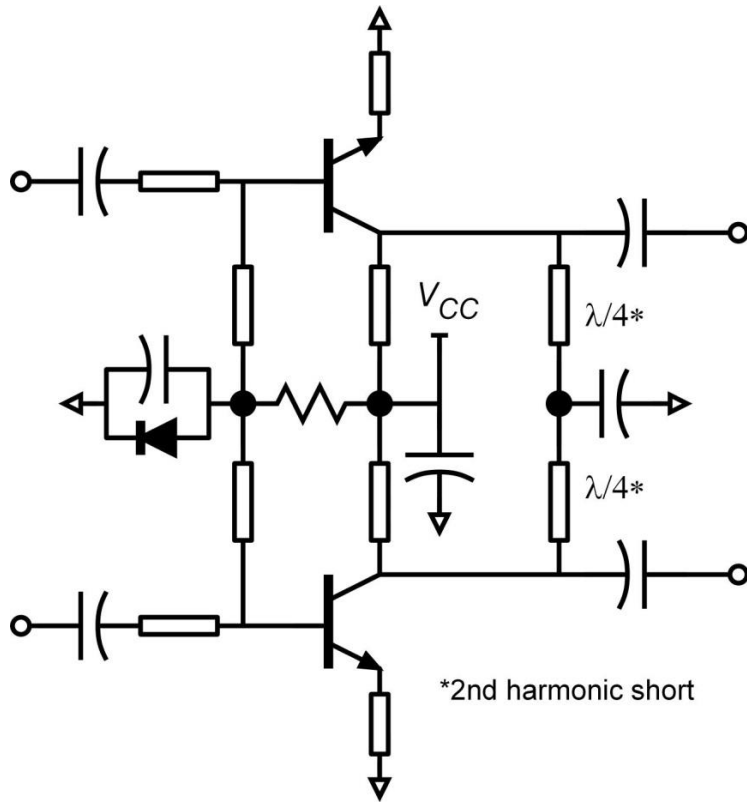
Potential problems with common mode \times

mm-wave common-mode instability



In all amplifiers, stability must be ensured from DC- f_{\max} .
Differential **& common-mode** stability must be ensured from DC- f_{\max}
Simple LNA inductive tuning is, for example, problematic

Pseudo-Differential Stages

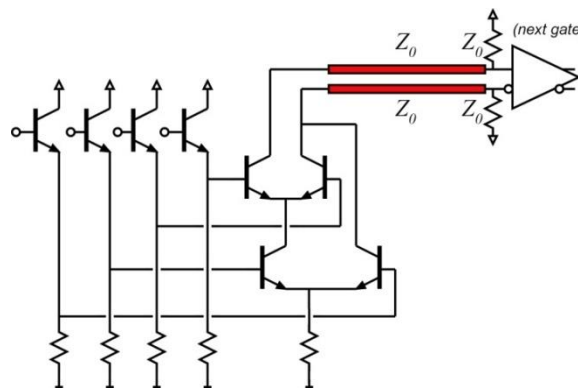



- No common-mode instability problem.
- Power-supply is virtual ground.
- No supply detuning of output network
- Improved power-supply isolation (oscillation, unwanted signal coupling)

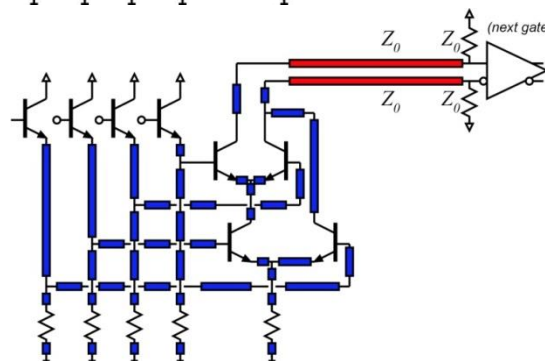
**20+ GHz
digital &
mixed-signal
design**

Modeling Interconnects: Digital & Mixed-Signal IC's

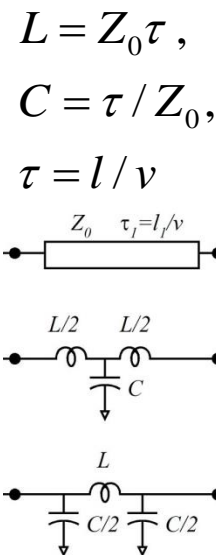
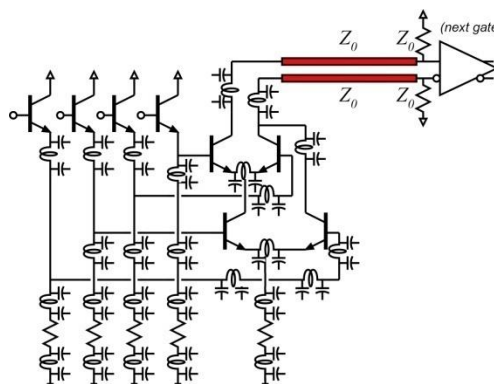
longer interconnects: 
lines terminated in Z_0 → no reflections.



Shorter interconnects: 
lines NOT terminated in Z_0 .
But they are *still* transmission-lines.
Ignore their effect at your peril !



If length \ll wavelength,
or line delay \ll risetime,
short interconnects behave
as lumped L and C .

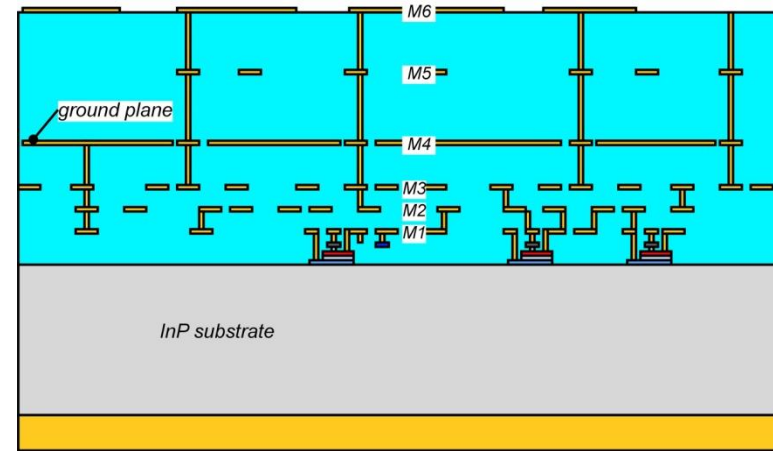


Modeling: 2.5D, library Tline, or L-C

Design Flow: Digital & Mixed-Signal IC's

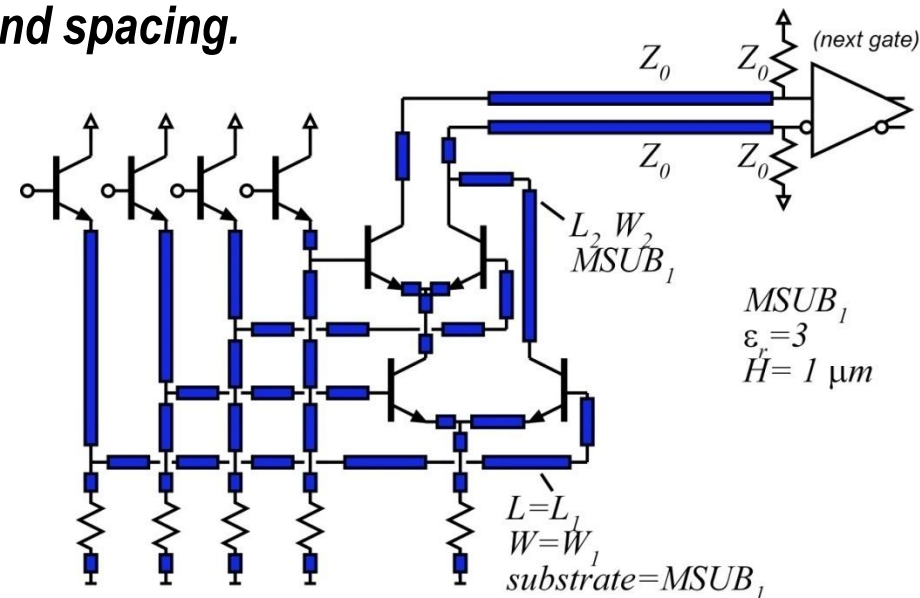
**All interconnects: thin-film microstrip environment.
Continuous ground on one plane.**

**2.5-D simulations run on representative lines.
various widths, various planes
same reference (ground) plane.**



**Simulation data manually fit to CAD line model
effective substrate ϵ_r , effective line-ground spacing.**

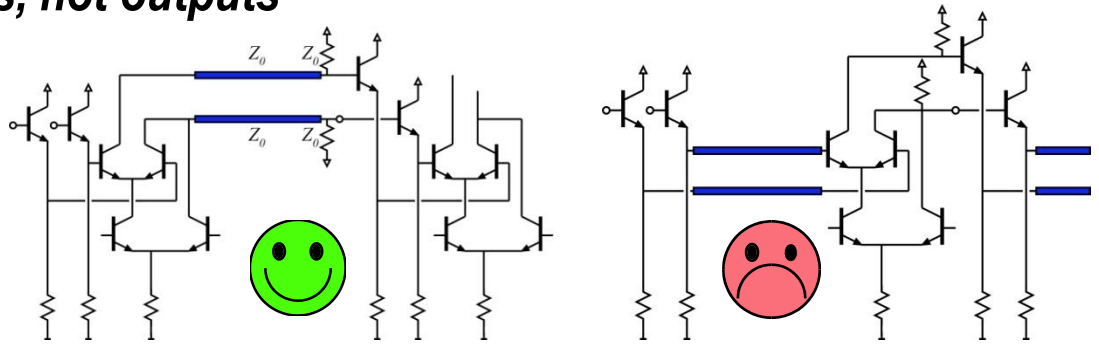
**Width, length, substrate of each line
entered on CAD schematic.
rapid data entry, rapid simulation.**



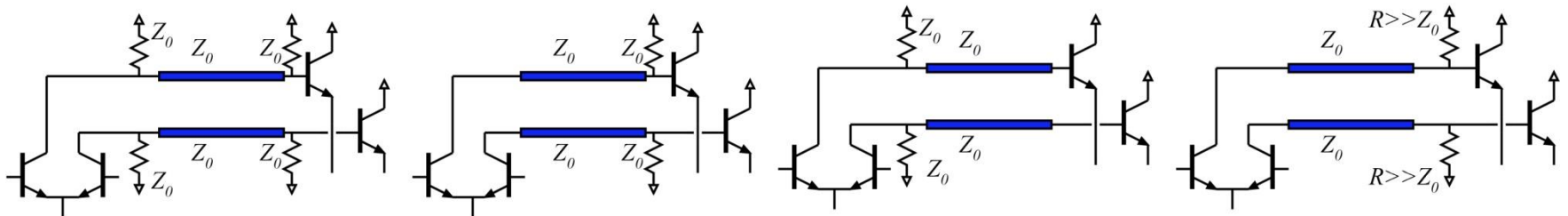
**Resistors and capacitors:
2.5-D simulation \rightarrow RLC fit
RLC model used in simulation.**

High Speed ECL Design

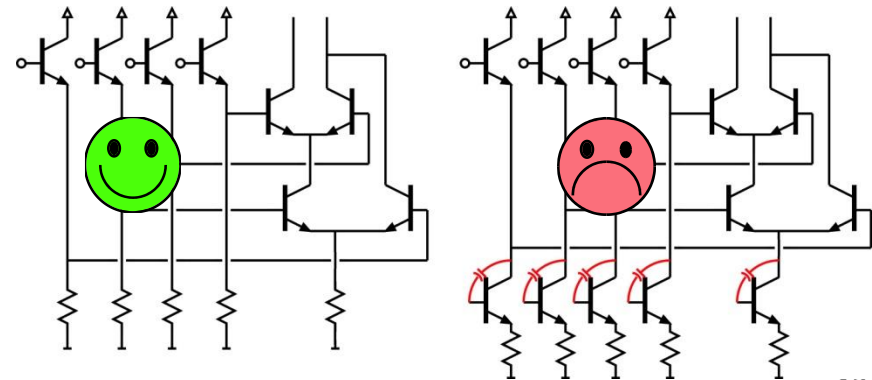
Followers associated with inputs, not outputs
Emitters never drive long wires.
(instability with capacitive load)



Double termination for least ringing, send or receive termination for moderate-length lines, high-Z loading saves power but kills speed.



Current mirror biasing is more compact.
Mirror capacitance → ringing, instability.
Resistors provide follower damping.

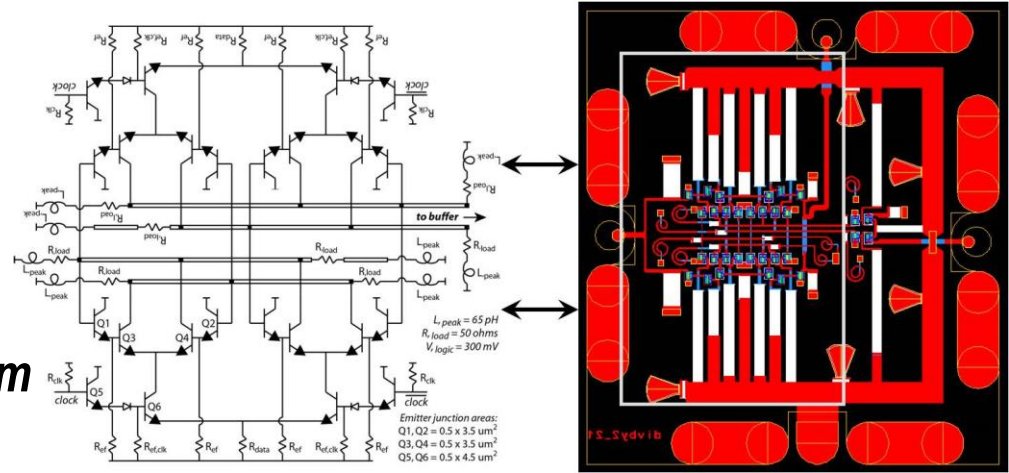


High Speed ECL Design

Layout: short signal paths at gate centers, bias sources surround core.
Inverted thin film microstrip wiring.

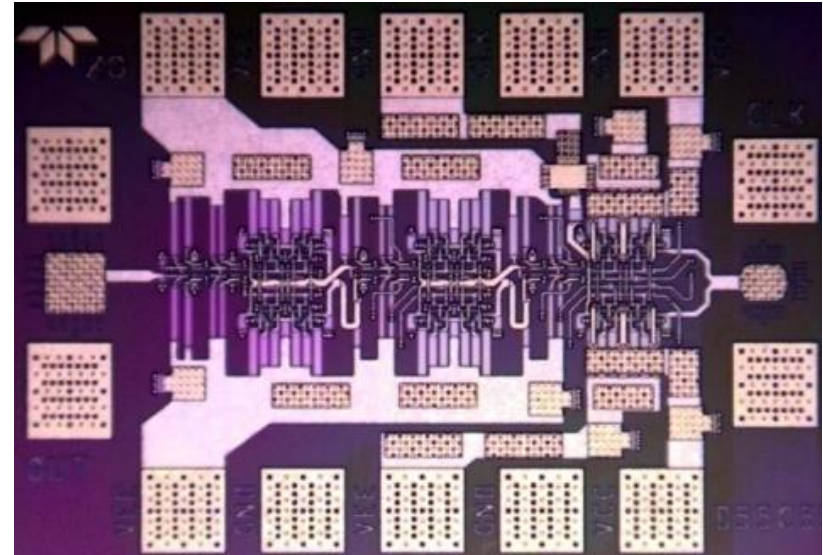
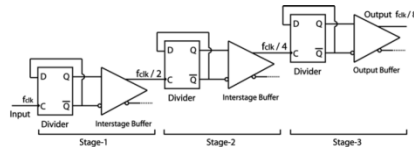
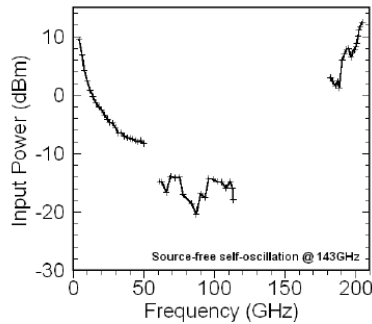
Key: transistors in on-state operate at Kirk limited-current.
 → minimizes C_{cb}/I_c delay.

Key: transistors designed for minimum ECL gate delay*, not peak (f_τ, f_{max}).
 *hand expression, charge-control analysis

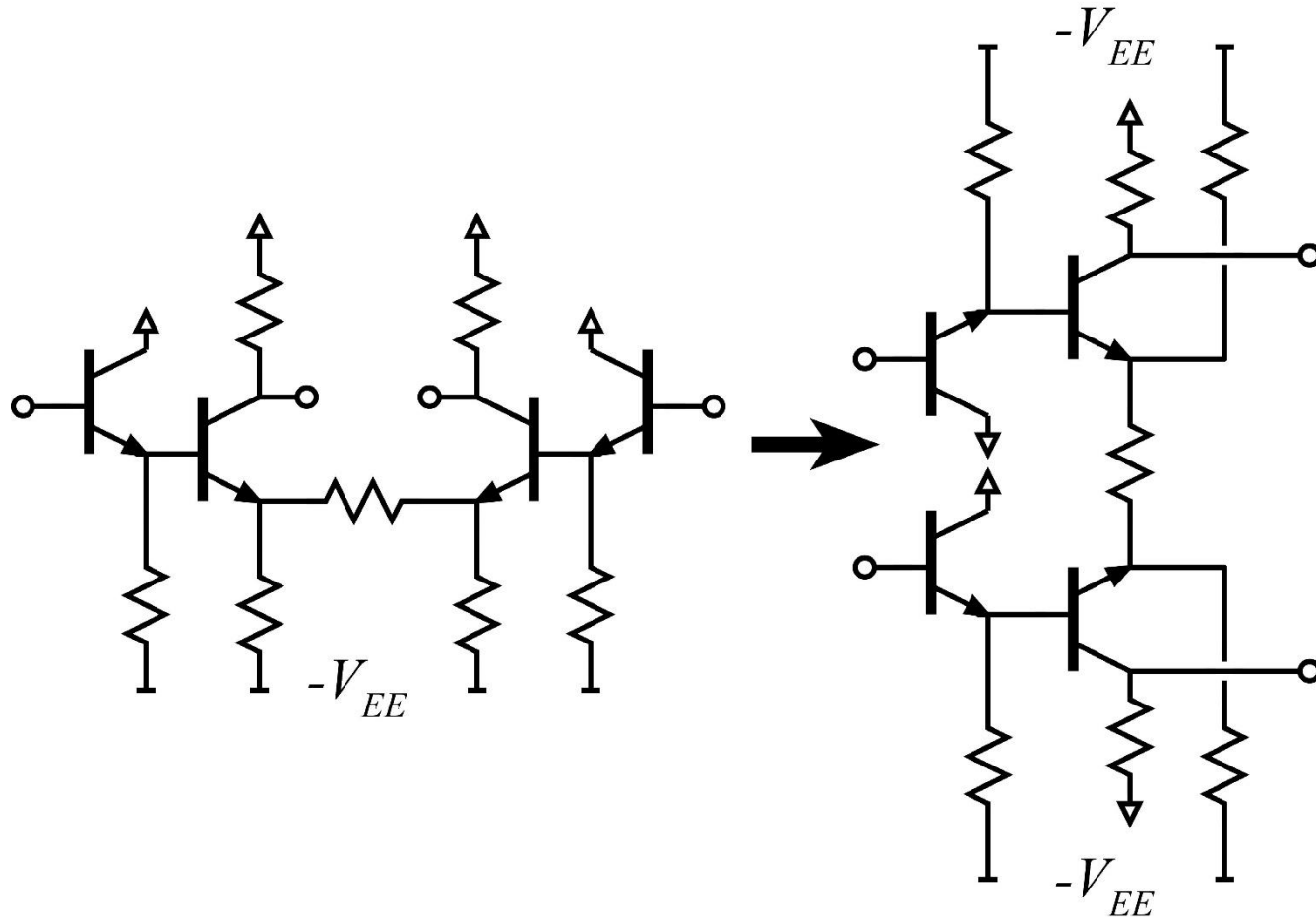


205 GHz divider, Griffith et al, IEEE CSIC, Oct. 2010

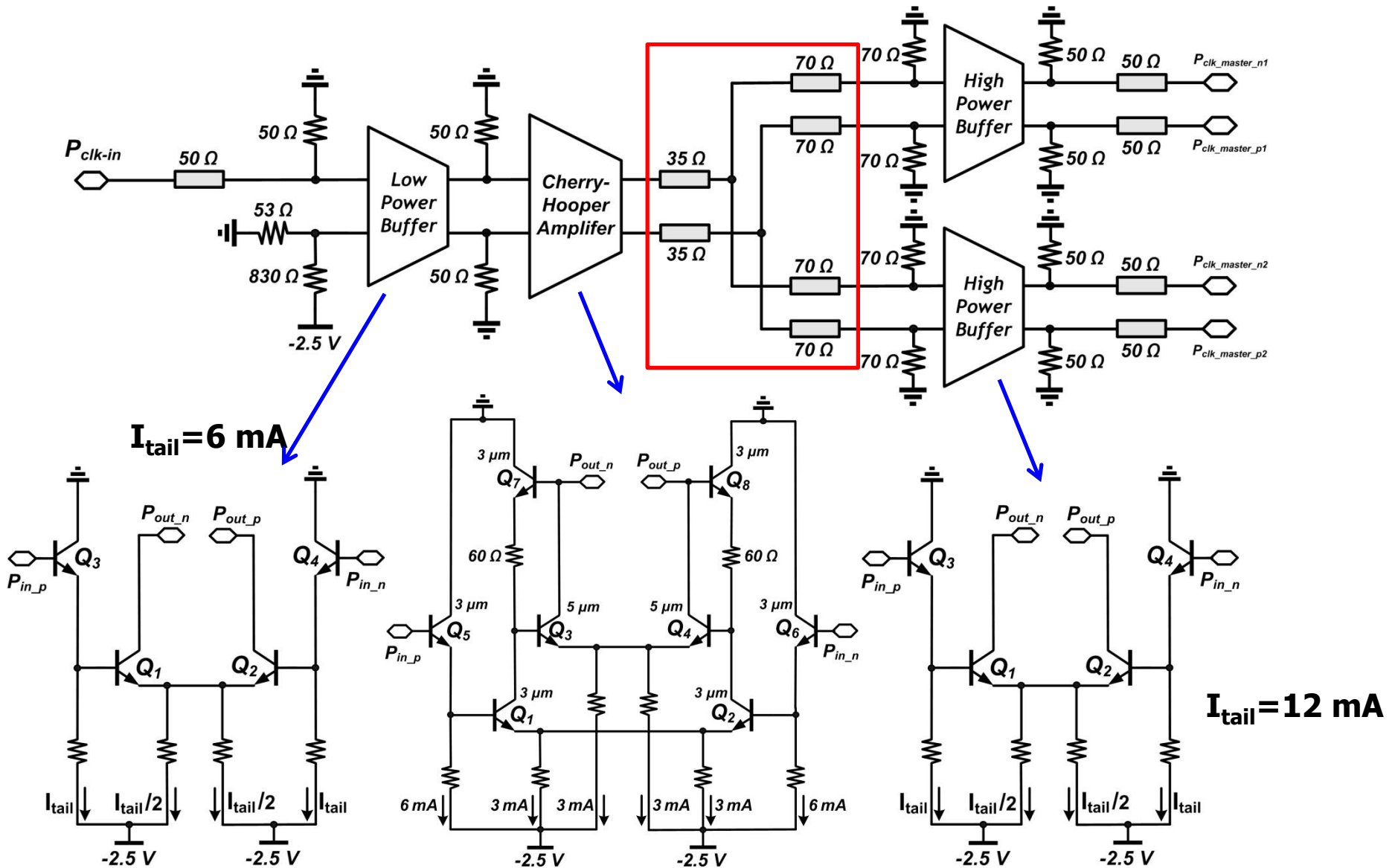
Example: 8:1 205 GHz static divider in 256 nm InP HBT.



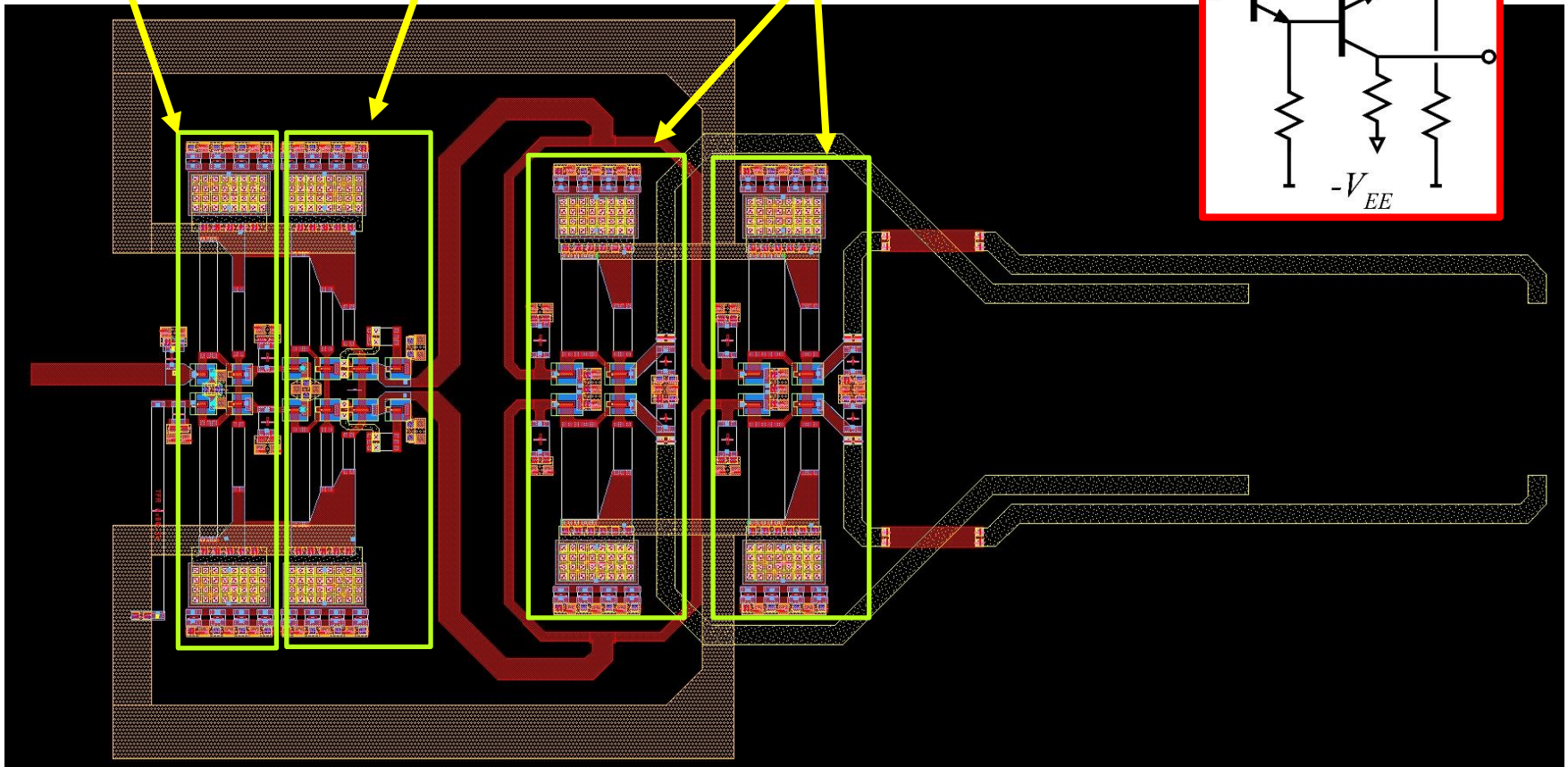
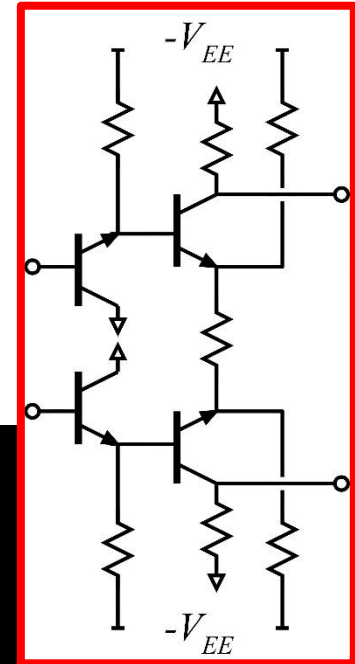
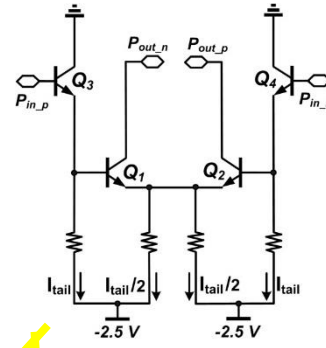
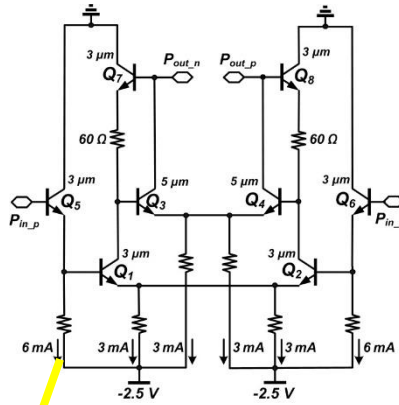
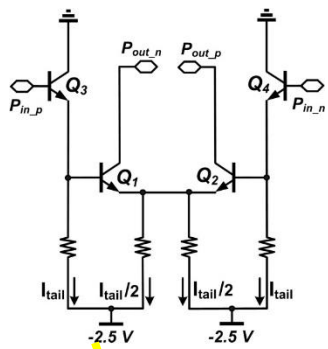
Differential stages: schematic vs. floorplan



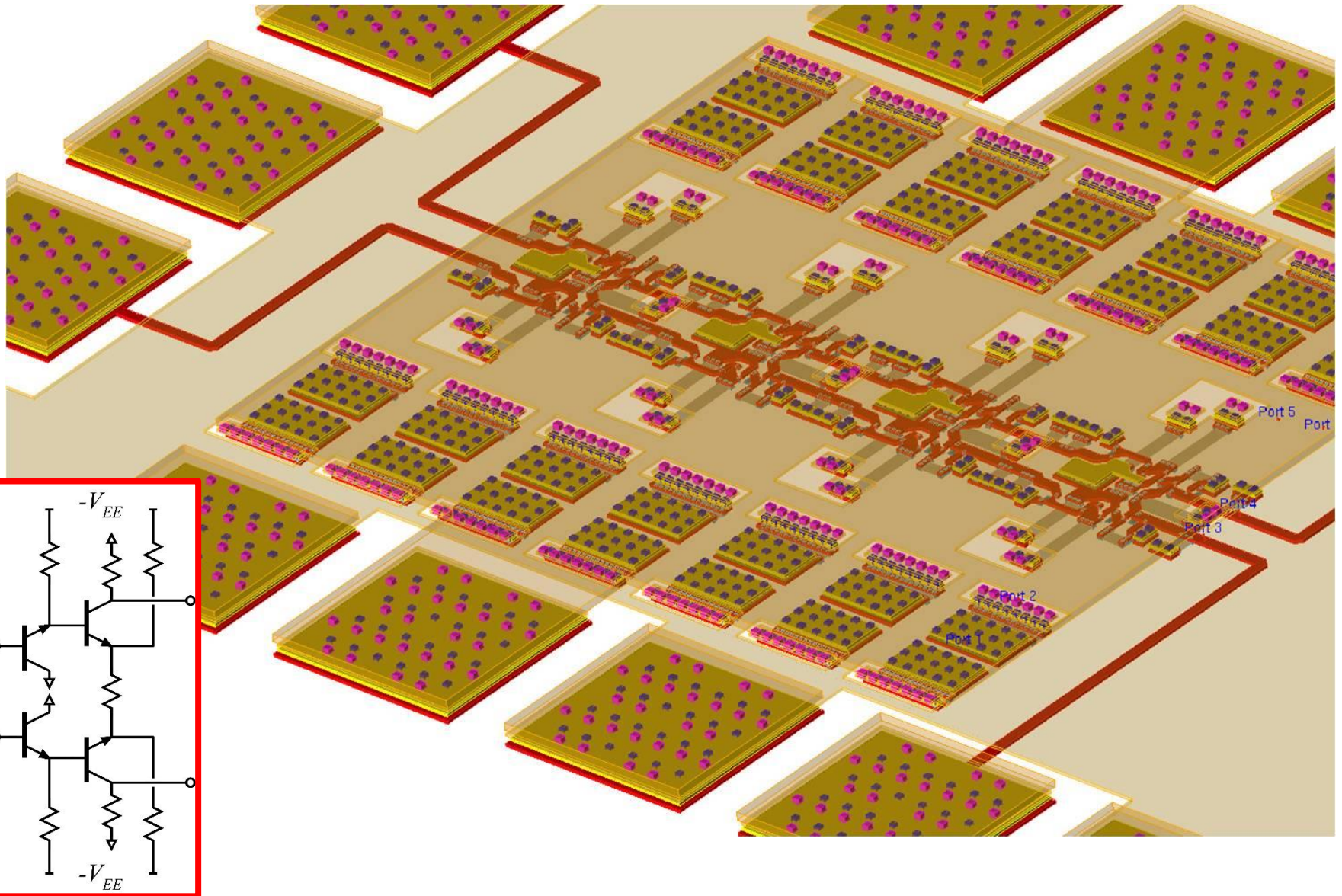
Example: 40 GS/s S/H clock buffer



Example: 40 GS/s S/H clock buffer



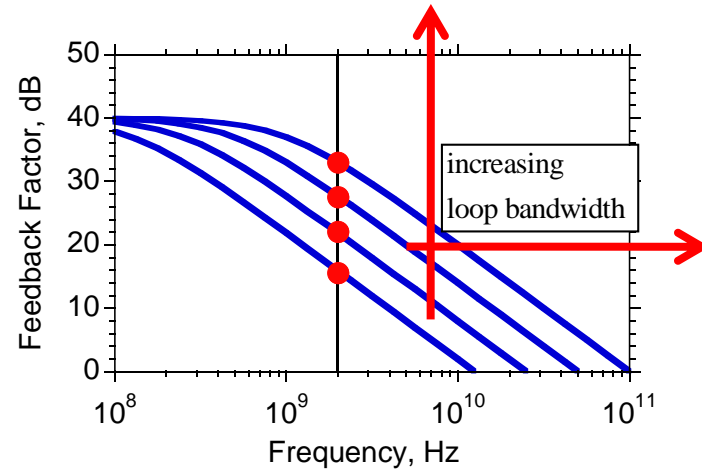
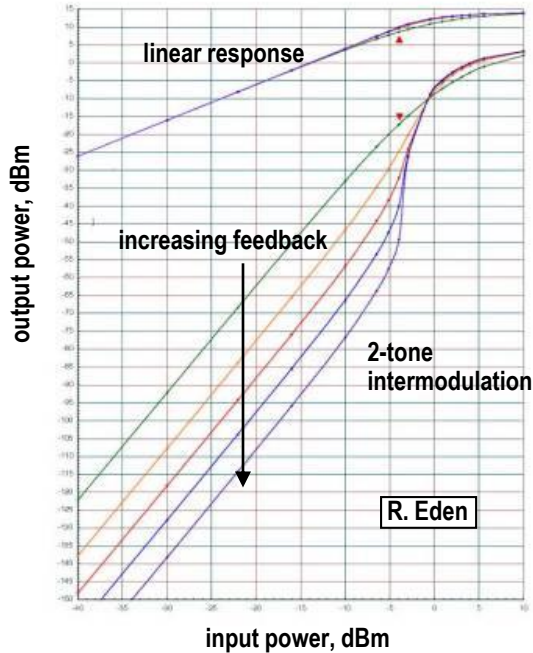
Example: 40 GS/s S/H clock buffer



20GHz Op-Amps for Linear 2 GHz Amplification

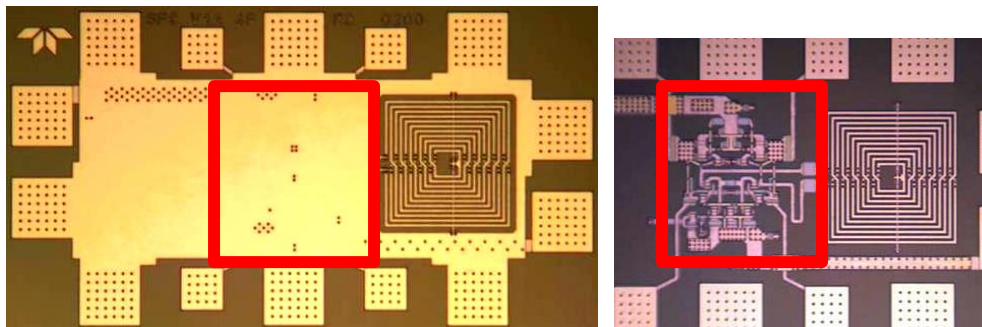
Griffith et al, IEEE IMS, June. 2011

Reduce distortion with strong negative feedback

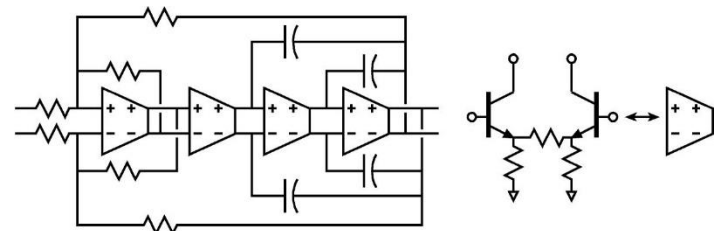


**Even for 2 GHz operation,
loop bandwidths must 20-40 GHz.**

need very fast transistors



**physically small feedback loop;
bias components surround active core.**



86 GHz Power Amplifier

mm-Wave Power Amplifier: Challenges

needed: High power / High efficiency / Small die area (low cost)

Extensive power combining

Compact power-combining

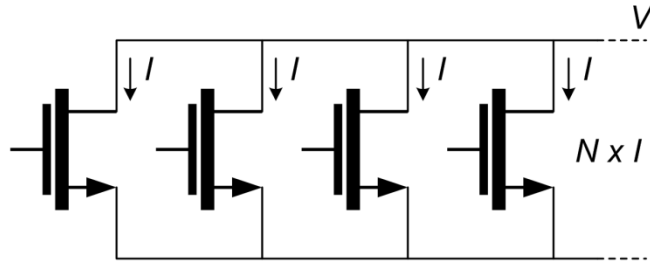
$$\text{PAE} = \eta_{\text{drain/collector}} \left(1 - \frac{1}{\text{Gain}} \right) \cdot \eta_{\text{power-combiner}}$$

Class E/D/F are poor @ mm-wave
insufficient f_{max} ,
high losses in harmonic terminations

Efficient power-combining

Goal: efficient, compact mm-wave power-combiners

Parallel Power-Combining

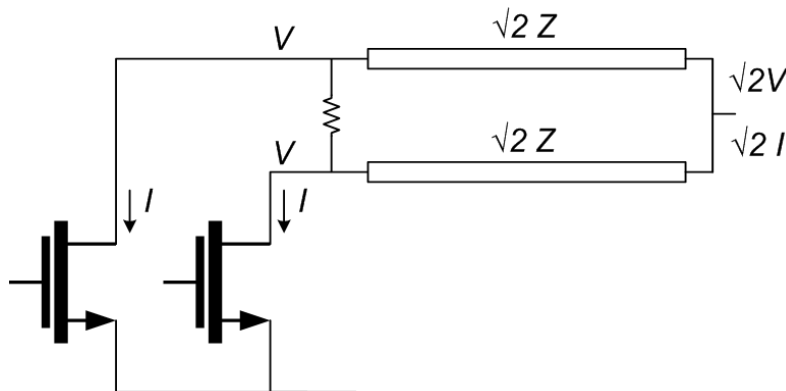


Output power: $P_{OUT} = N \times V \times I$

Parallel connection increases P_{OUT} ✓

Load Impedance: $Z_{OPT} = V / (N \times I)$

Parallel connection decreases Z_{opt} ✗



High $P_{OUT} \rightarrow$ Low Z_{opt}

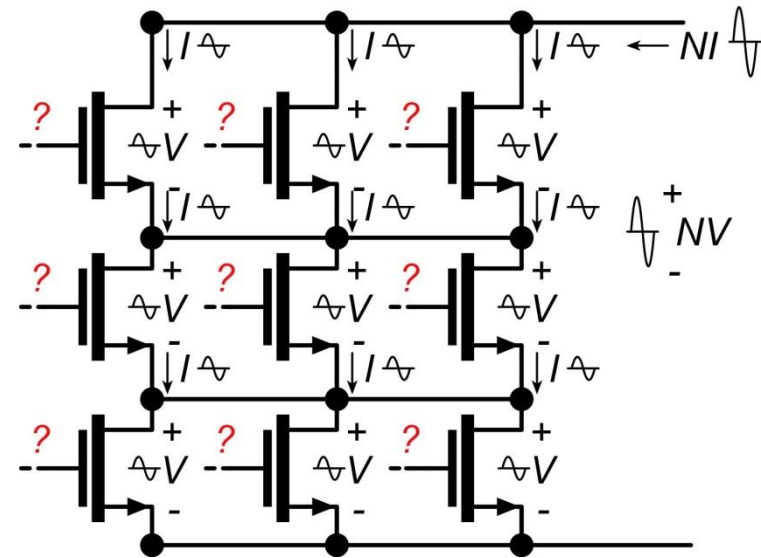
Needs impedance transformation:
lumped lines, Wilkinson, ...

High insertion loss ✗

Small bandwidth

Large die area

Series Power-Combining & Stacks



Parallel connections: $I_{out} = N \times I$

Series connections: $V_{out} = N \times V$

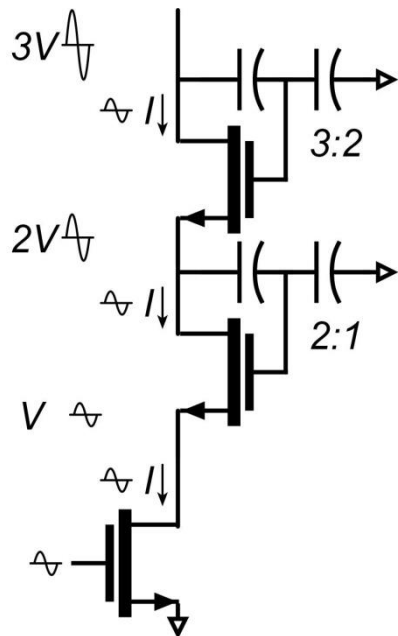
Output power: $P_{out} = N^2 \times V \times I$

Load impedance: $Z_{opt} = V/I$ ✓

Small or zero power-combining losses ✓

Small die area ✓

How do we drive the gates ?



Local voltage feedback:
drives gates, sets voltage distribution

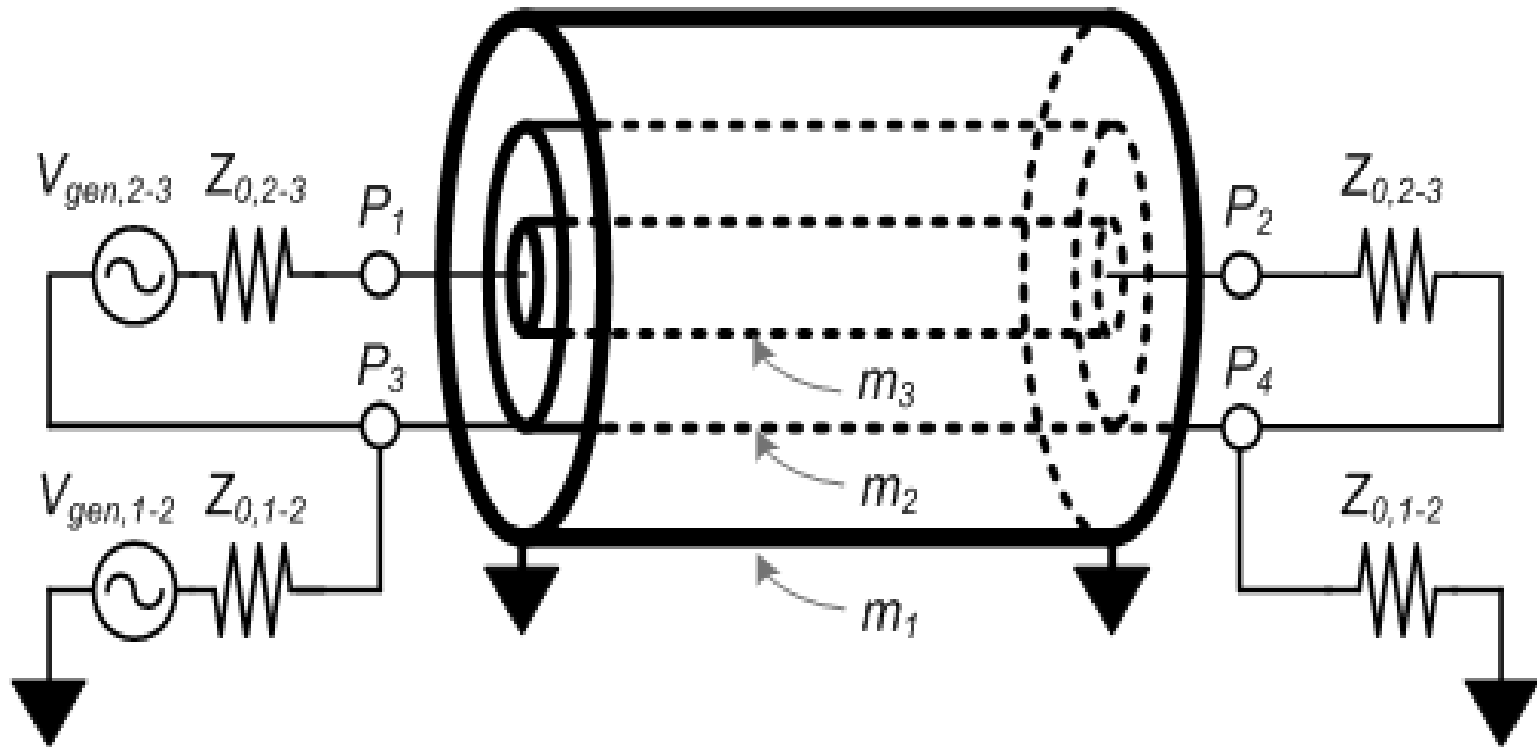
Design challenge:

need uniform RF voltage distribution

need ~unity RF current gain per element

...needed for simultaneous compression of all FETs.

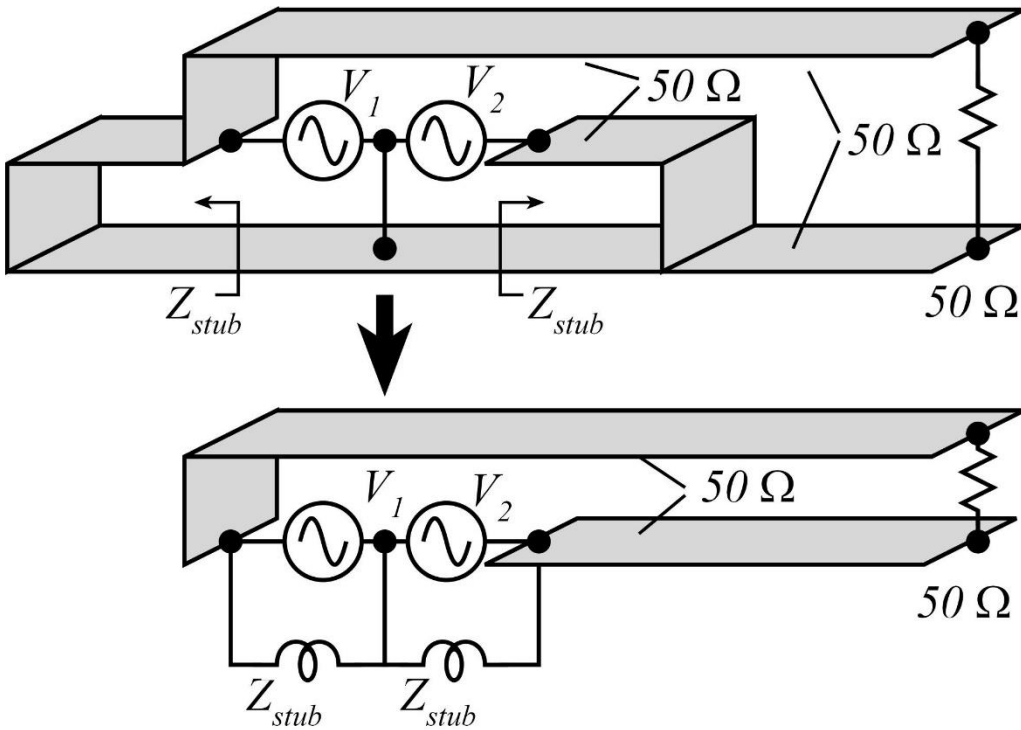
Ideal Tri-axial Line



Two separate transmission lines (m_3 - m_2 , m_2 - m_1)

→ E, H fields between m_3 and m_1 perfectly shielded

Sub- $\lambda/4$ Baluns for **Series** Combining



Balun combiner:

2:1 series connection ✓

each source sees $25\ \Omega$

→ 4:1 increased P_{out} ✓

Standard $\lambda/4$ balun :

long lines

→ high losses ✗

→ large die ✗

Sub- $\lambda/4$ balun :

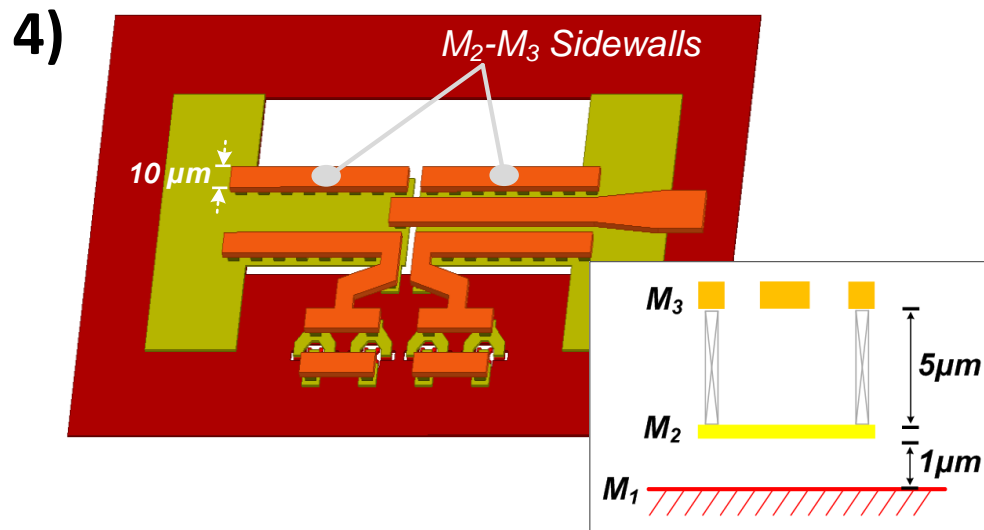
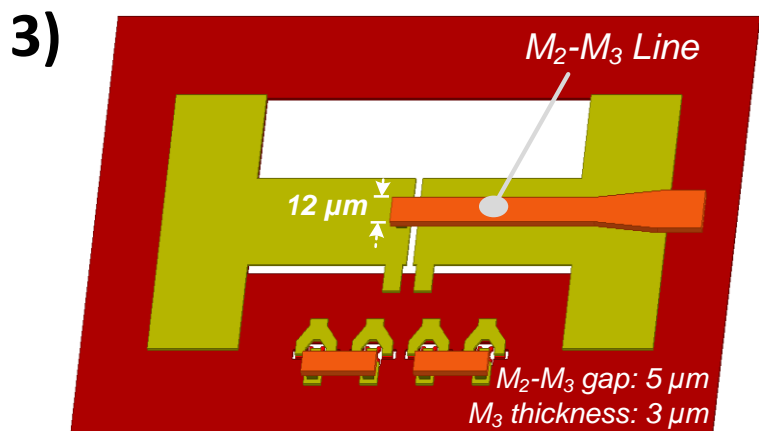
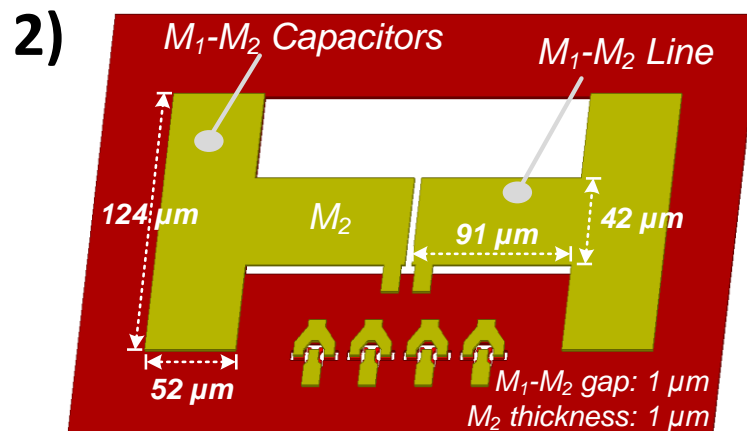
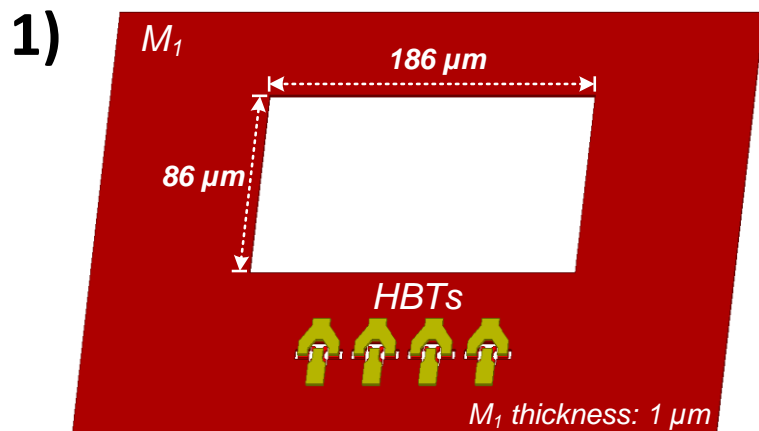
stub → inductive

tunes transistor C_{out} ! ✓

short lines → low losses ✓

short lines → small die ✓

Baluns in Real ICs



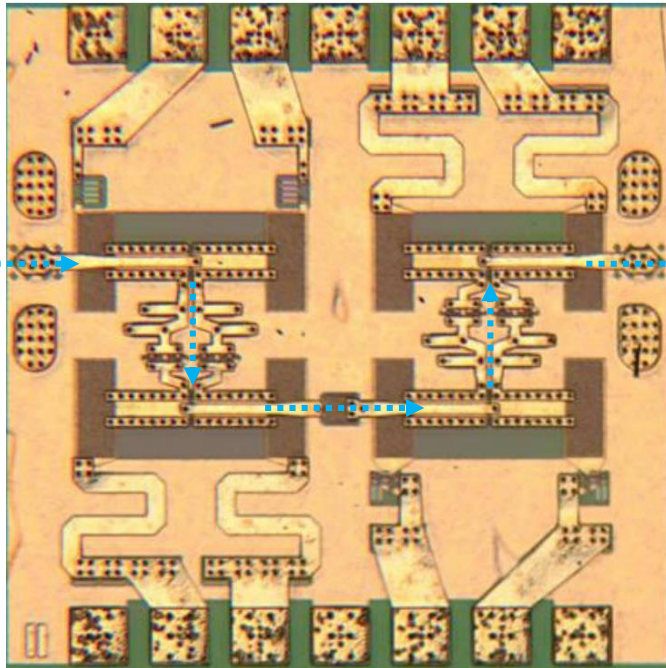
1) M_1 as a GND

2) Slot-type transmission lines (M_1 - M_2), AC short (2 pF MIM)

3) Microstrip line (M_2 - M_3), E-field shielding **NOT** negligible

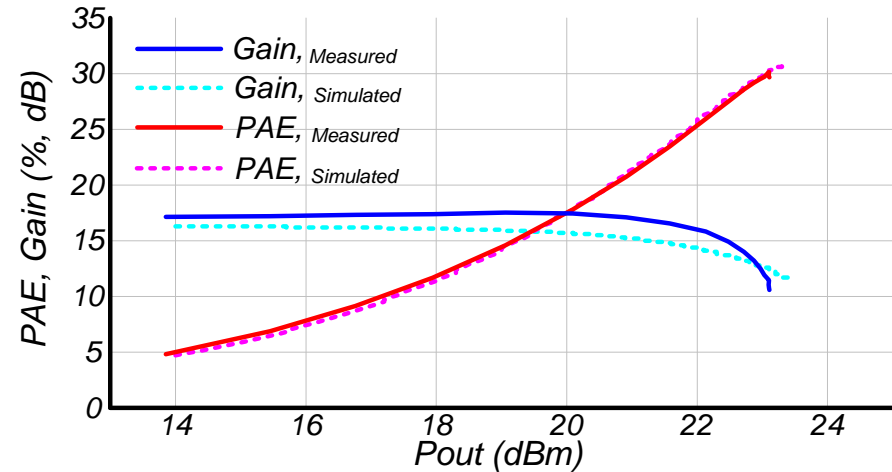
4) **Sidewalls** between M_3 - M_1 (Faraday cages), **$\lambda/16$ length**

Two-Stage PA IC Test Results (86GHz)



IC size: 825 x 820 μm^2

Large signal measurements



Gain: 17.5 dB

P_{SAT} : >200 mW @ 3.0 V

PAE: >30 %

Power density (power/die area)
= 307 mW/mm² (including RF pads)
= 927 mW/mm² (core area)

[H. Park et al, CSICS 2013]

30% PAE W-Band InP Power Amplifiers Using Sub-Quarter-Wavelength Baluns for Series-Connected Power-Combining

4:1 series-connected 81GHz power amplifier

Park et al., 2014 IEEE-IMS

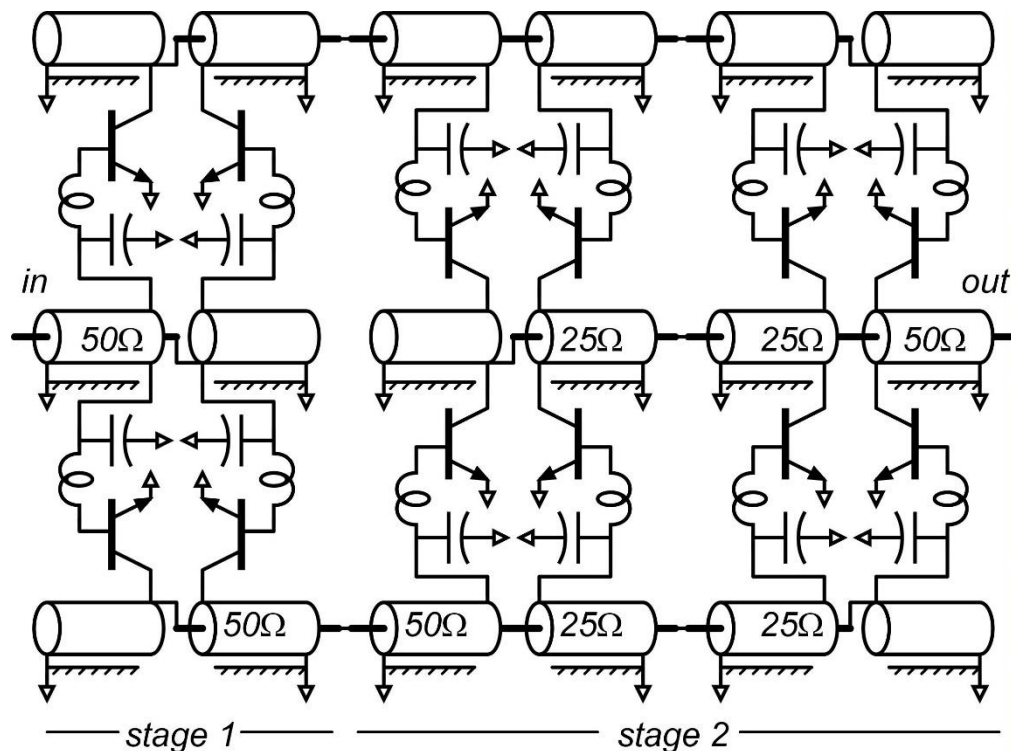
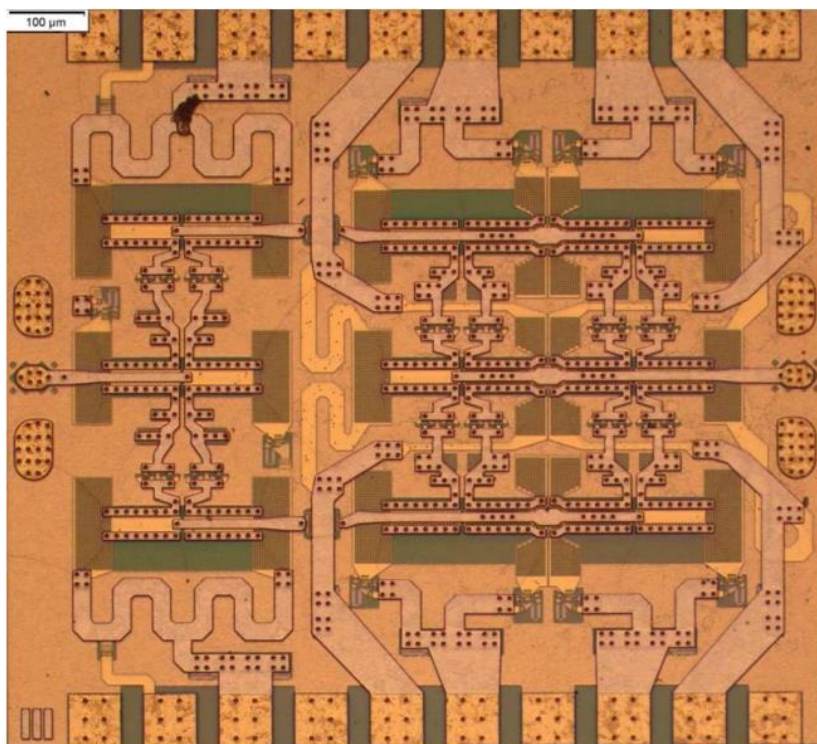
17 dB Gain

470 mW P_{sat}

23% PAE

Teledyne 250 nm InP HBT

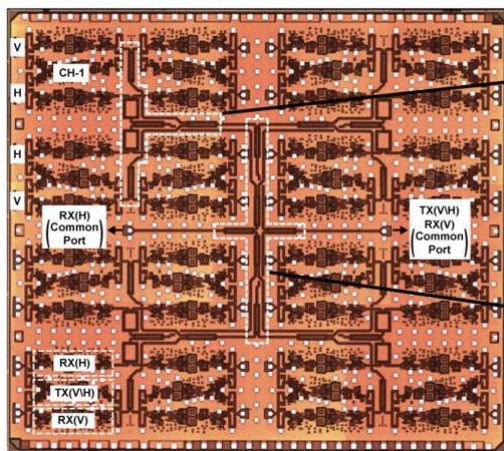
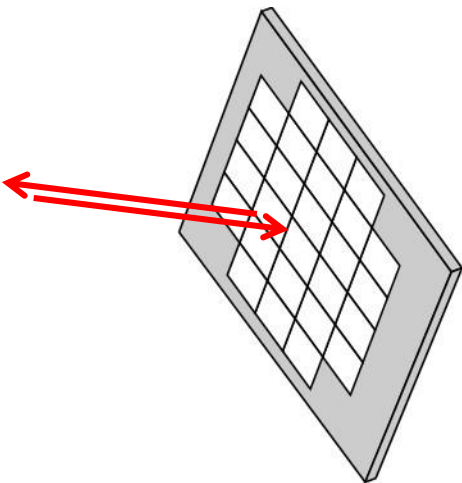
2 stages, 1.0 mm²(incl pads)



**IC example:
220 GHz
power amplifier**

Millimeter-wave imaging

10,000-pixel, 94GHz imaging array → 10,000 elements



Golcuk: Trans MTT, Aug 2014

Demonstrated:

SiGe (UCSD/Rebeiz)

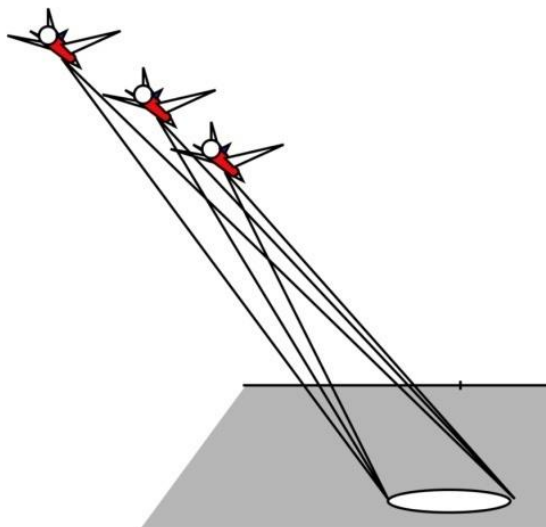
~1.3kW: 10,000 elements

Lower-power designs:

InP, CMOS, SiGe

(UCSB, UCSD, Virginia Poly.)

235 GHz video-rate synthetic aperture radar



1 transmitter, 1 receiver

100,000 pixels

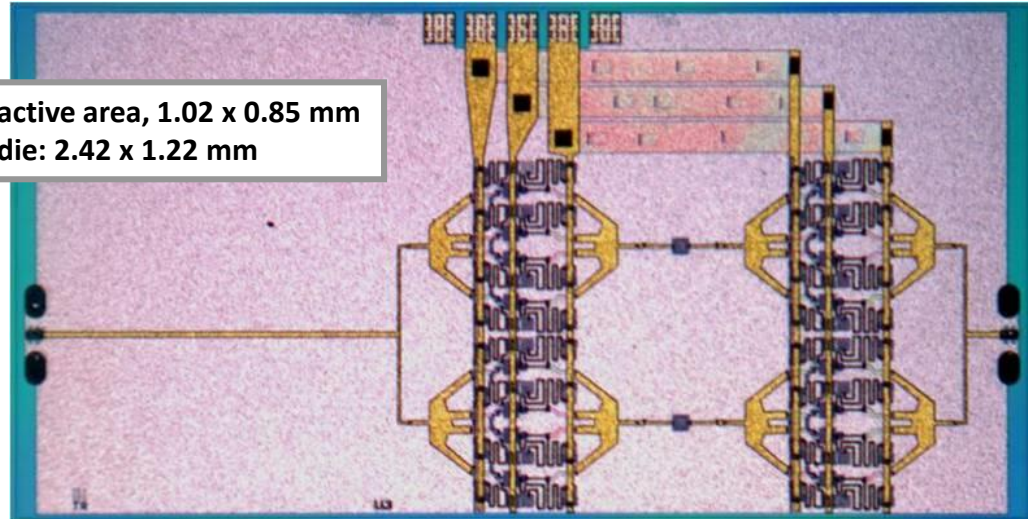
20 Hz refresh rate

5 cm resolution @ 1km

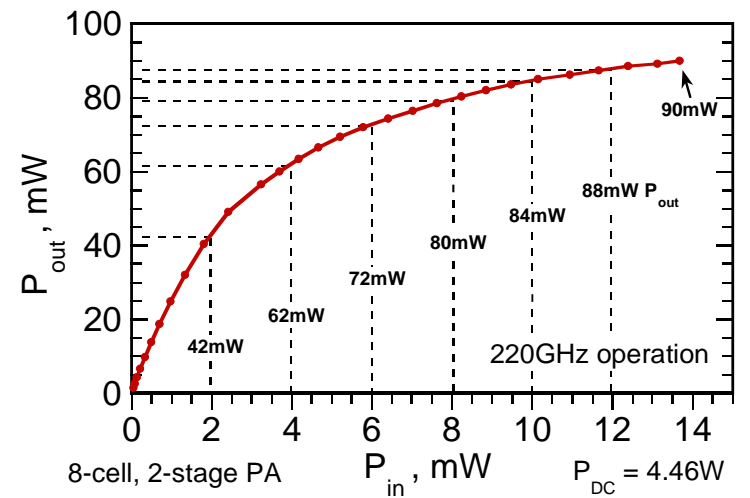
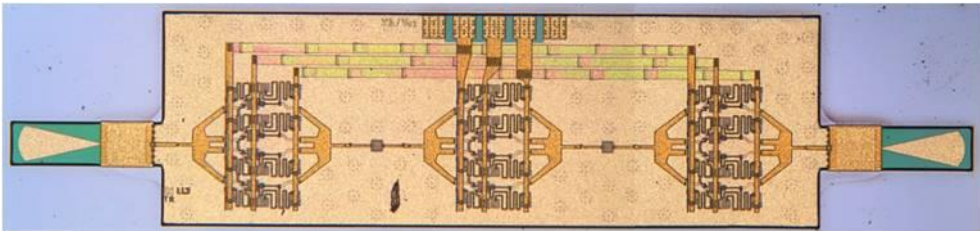
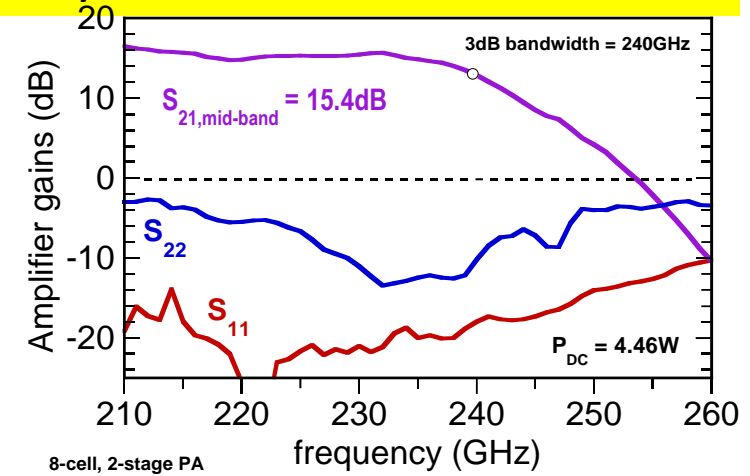
50 Watt transmitter

(tube, solid-state driver)

90 mW, 220 GHz Power Amplifier



Reed (UCSB) and Griffith (Teledyne): CSIC 2012
Teledyne 250 nm InP HBT



214 GHz InP HBT Power Amplifier

UCSB/Teledyne

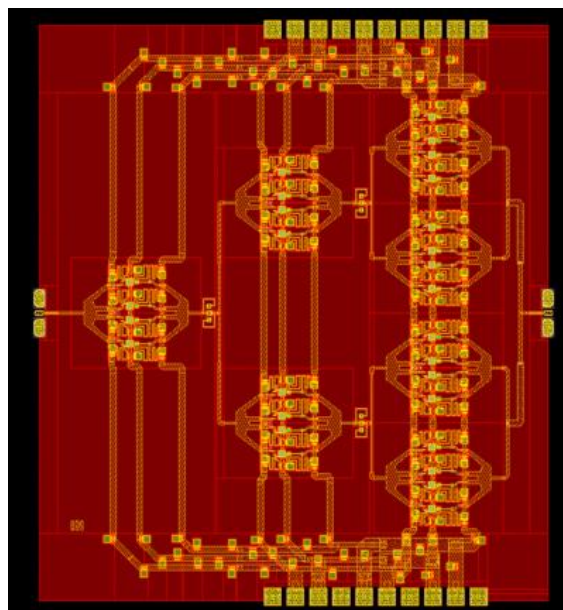
Gain: 25dB S21 Gain at 220GHz

Saturated output power: 164mW at 214GHz

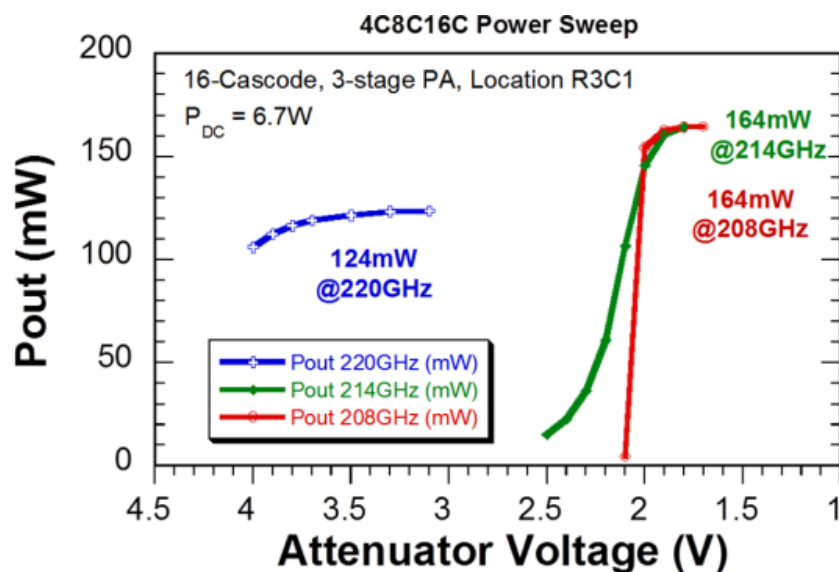
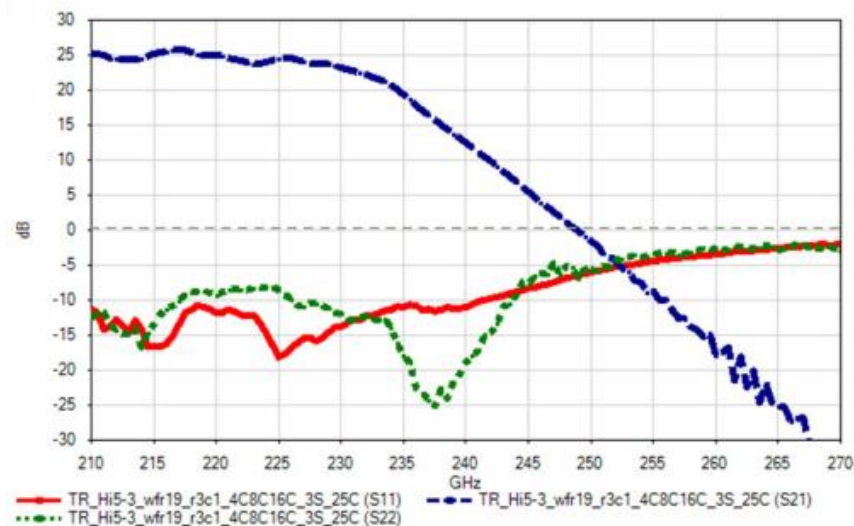
Output Power Density: 0.43 W/mm

PAE: 2.4%

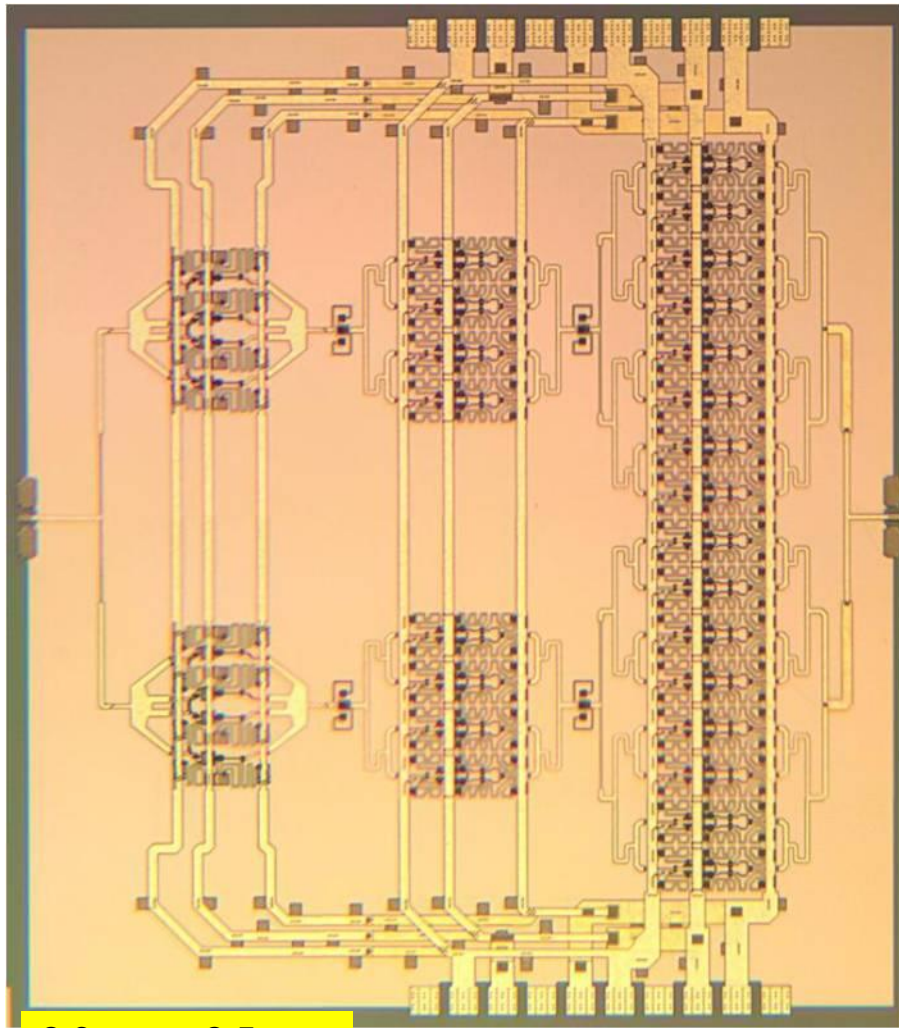
Technology: 250 nm InP HBT



(no die photo) 2.5mm x 2.1 mm

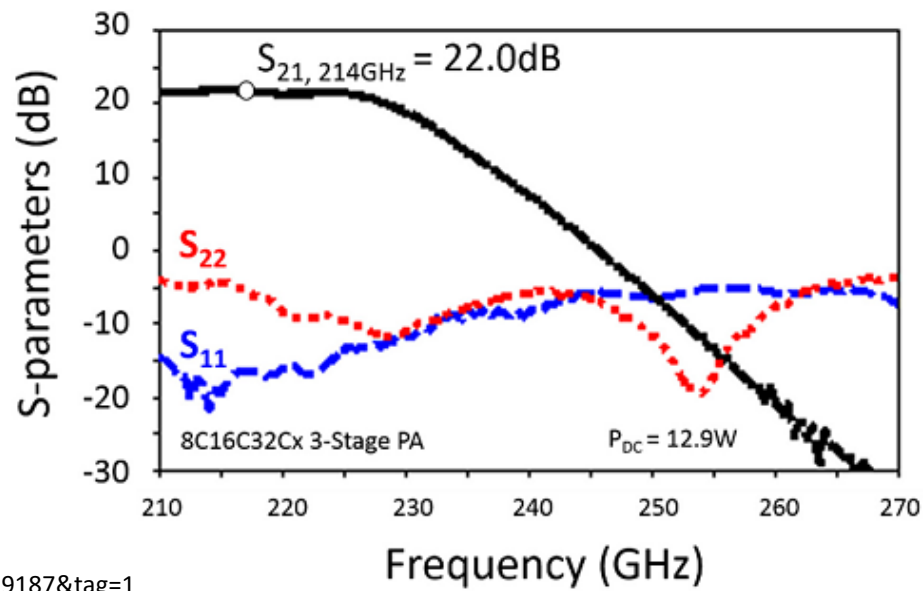
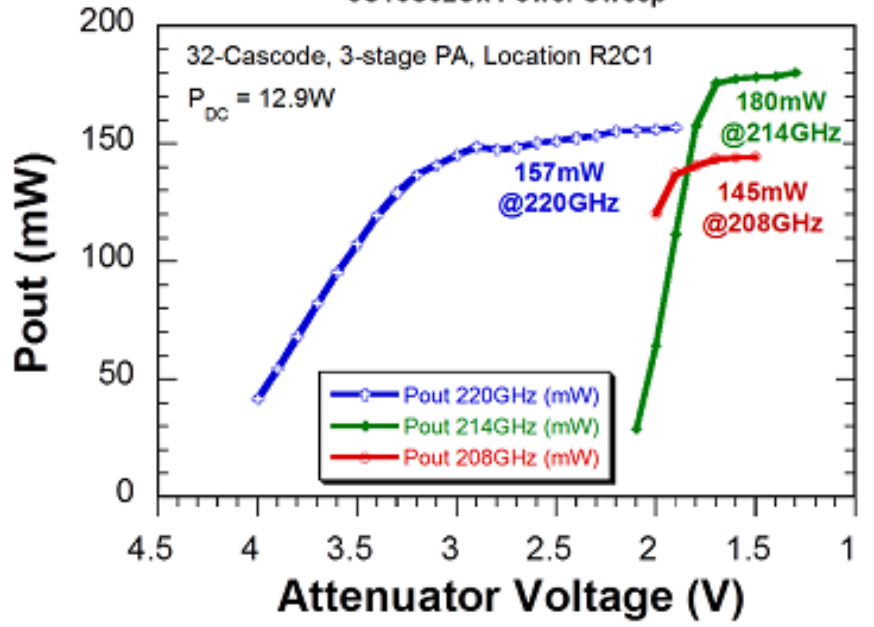


214 GHz 180mW Power Amplifier (330 mW design)

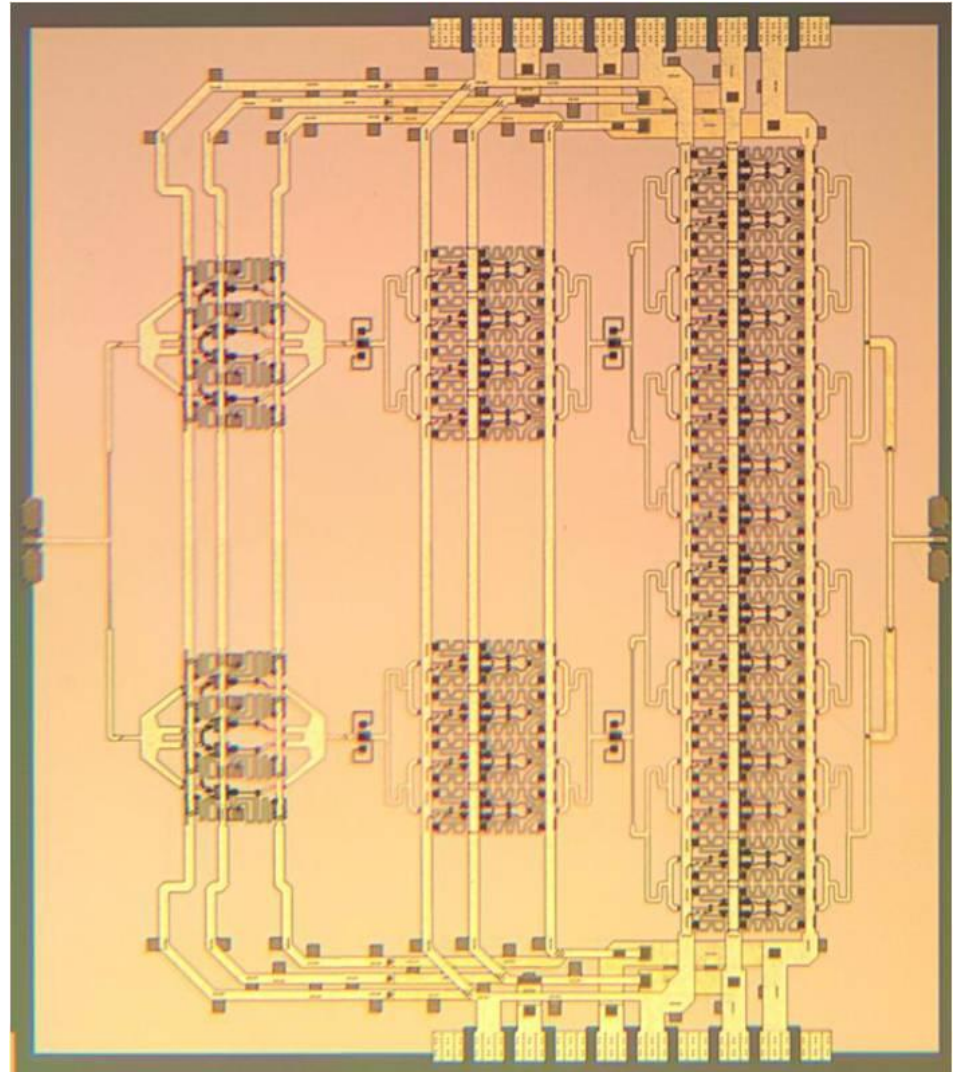
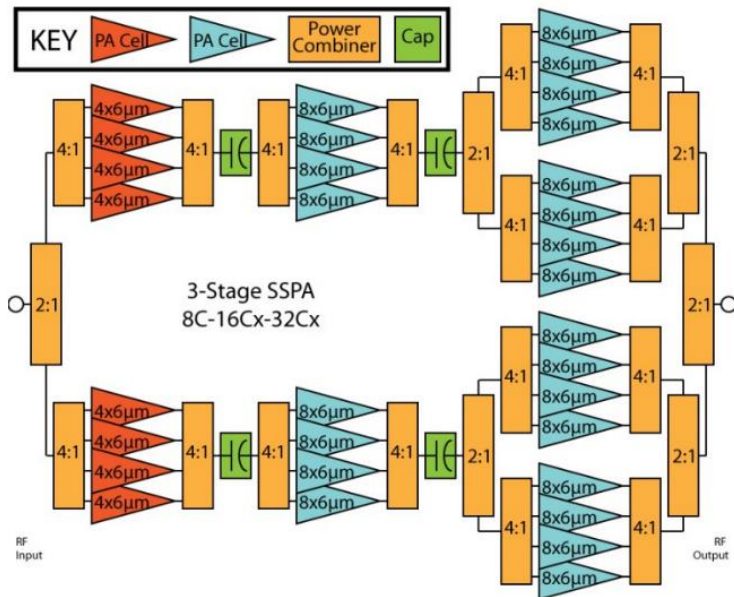
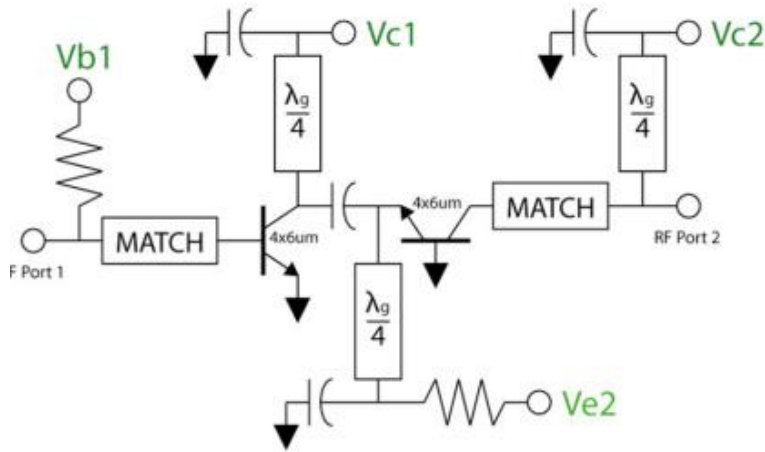


2.3 mm x 2.5 mm

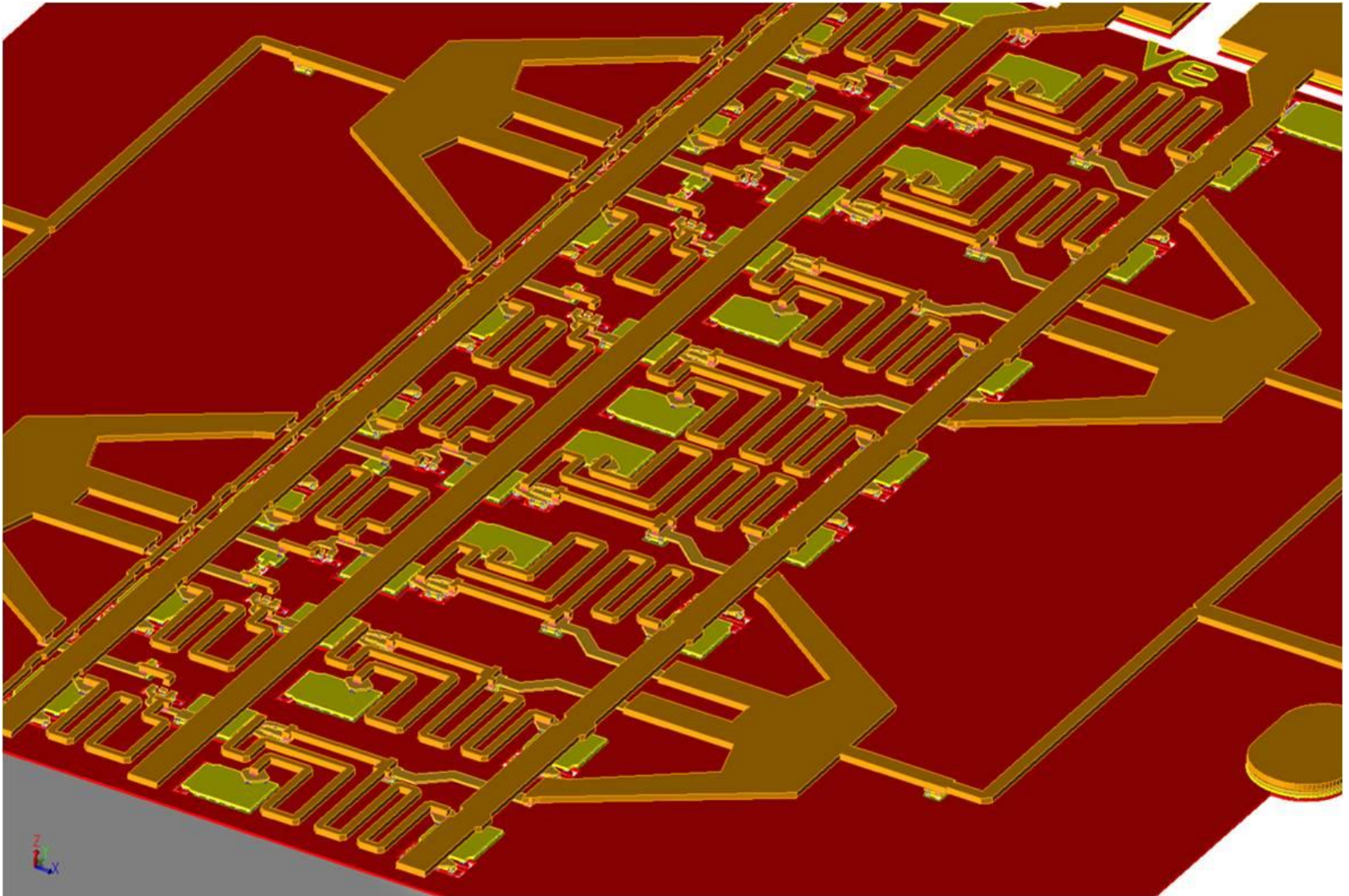
Reed, Griffith CSICS2013
Teledyne 250 nm InP HBT



220 GHz power amplifiers; 256nm InP HBT



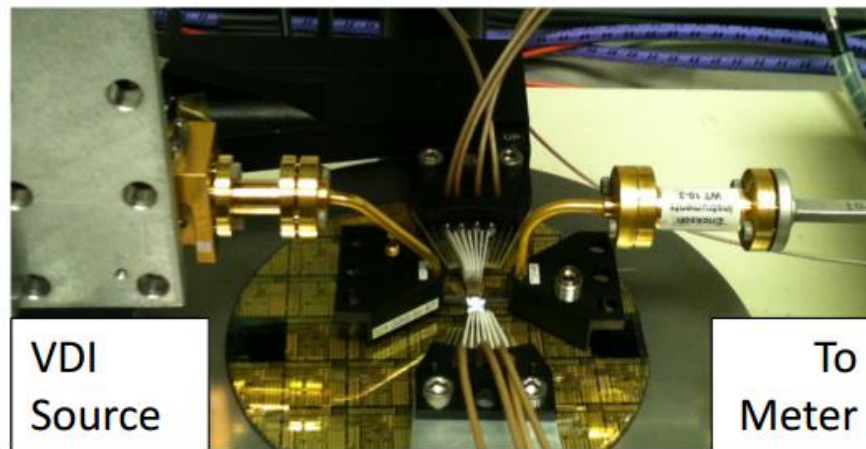
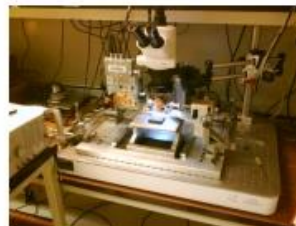
ICs in Thin-Film (Not Inverted) Microstrip



Note breaks in ground plane at transistors, resistors, capacitors

220 GHz measurement

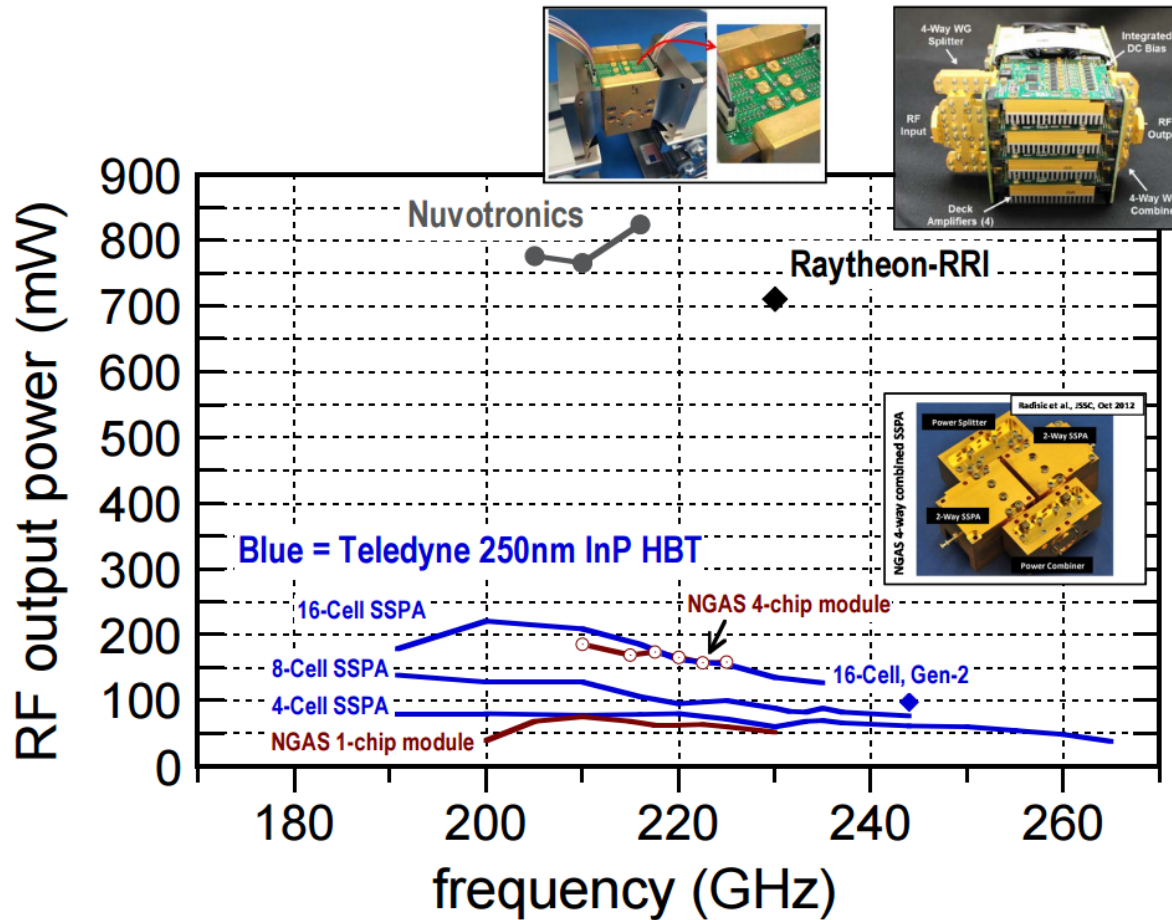
- **Small Signal Measurement**
 - VNA with 140-220 and 206-340 GHz frequency extender heads
 - LRRM Probe-tip Calibration
- **Power Sweep Measurement**
 - 220 GHz frequency multiplier chains and sub-mm wave power meter
 - Insertion Loss Calibration
 - Forced Air cooling



Power combined modules

Slide from Z. Griffith IMS 2016 Presentation

Summary of state-of-the-art WR04-band SSPAs

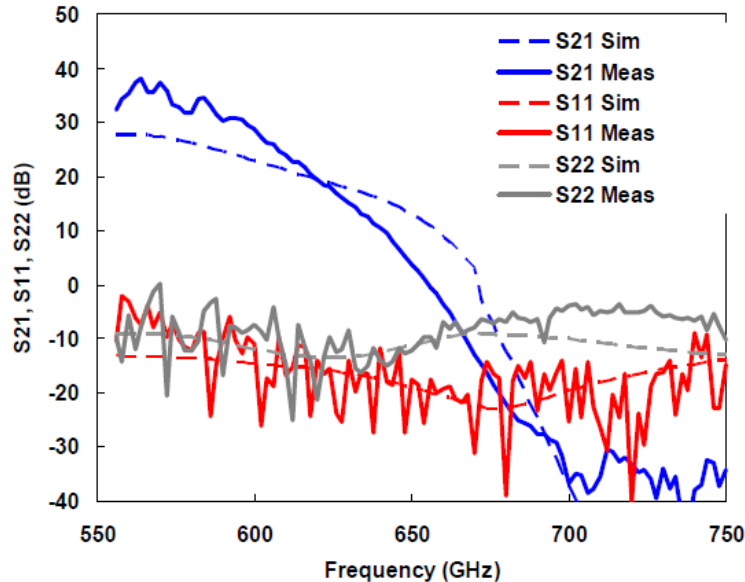


mm-Wave power

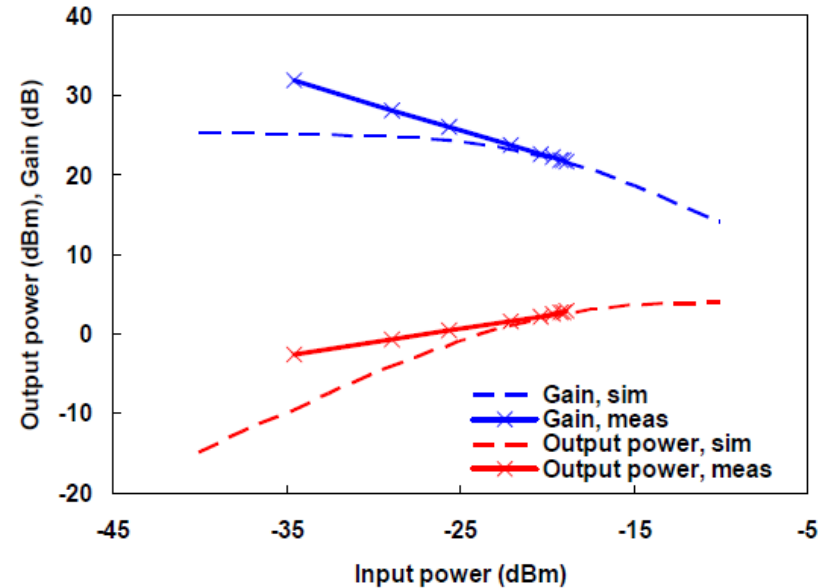
Teledyne: 1.9 mW, 585 GHz Power Amplifier

M. Seo *et al.*, Teledyne Scientific: IMS2013

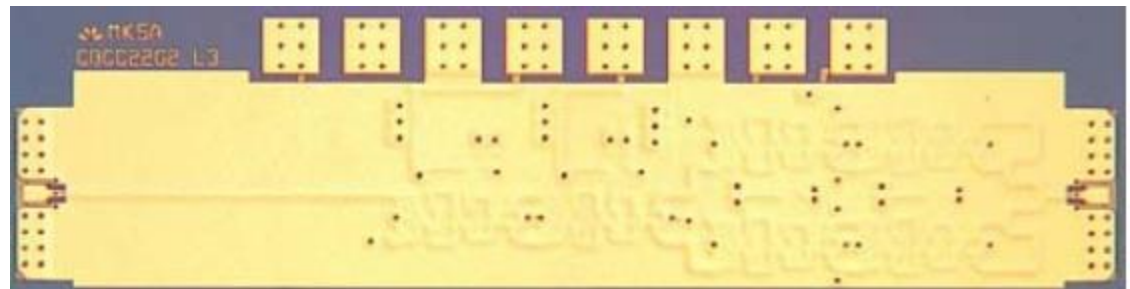
S-parameters



Output Power



- 12-Stage Common-base
- 2.8 dBm P_{sat}
- >20 dB gain up to 620 GHz



What limits output power in sub-mm-wave amplifiers ?

Sub-mm-wave PAs: need more current !

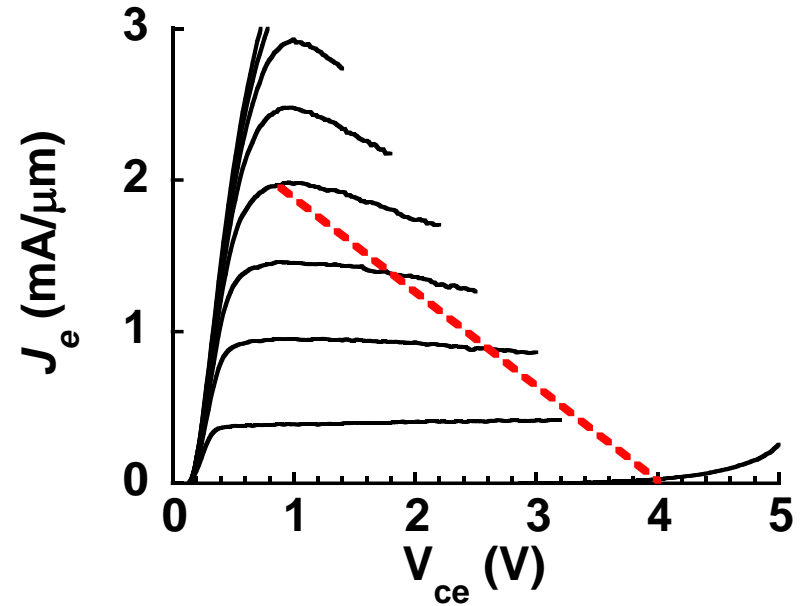
3 μm max emitter length ($> 1 \text{ THz } f_{\text{max}}$)

2 mA/ μm max current density

$$I_{\text{max}} = 6 \text{ mA}$$

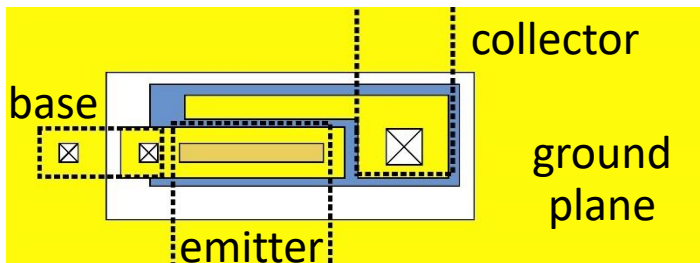
Maximum 3 Volt p-p output

$$\text{Load: } 3\text{V}/6\text{mA} = 500 \Omega$$

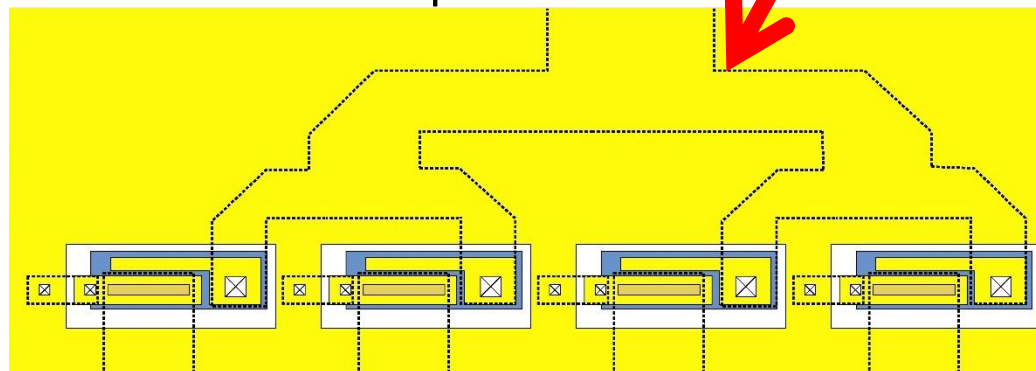


Combiner cannot provide 500 Ω loading

common-base HBT



HBTs with microstrip combiner



Multi-finger HBTs: more current, lower f_{\max}

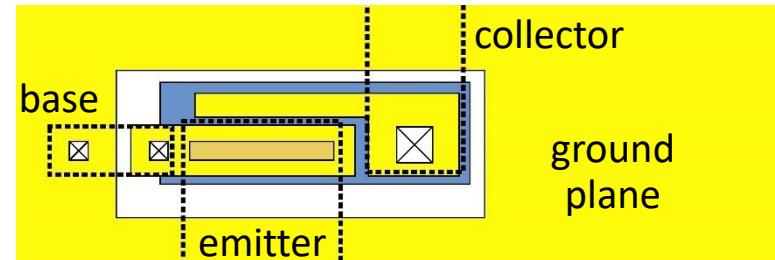
More current

→ lower cell load resistance

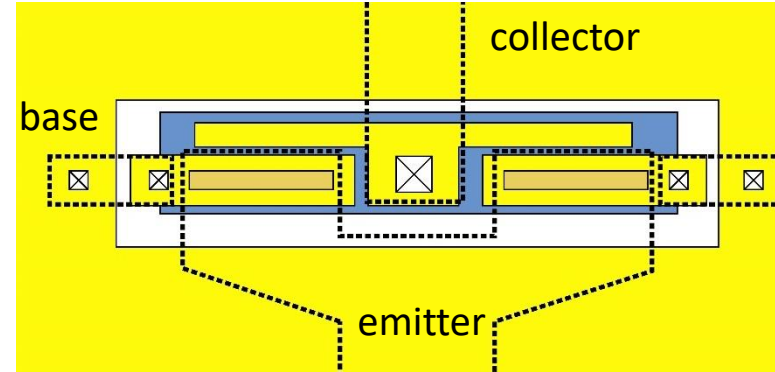
Reduced f_{\max} , reduced RF gain:
common-lead inductance → Z_{12}
feedback capacitance → Y_{12}
phase imbalance between fingers.

Worse at higher frequencies:
less tolerant of cell parasitics
less current per cell
higher required load resistance
Can optimum load be reached ?

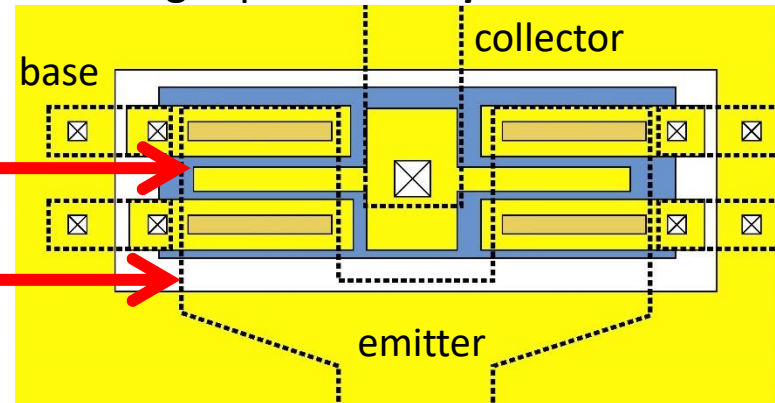
one-finger common-base HBT



two-finger power cell



four-finger power cell: *parasitics*



Sub-mm-wave transistors: need more current

InP HBTs:

thinner collector → more current
hotter → improve heat-sinking
or: longer emitters → thicker base metal

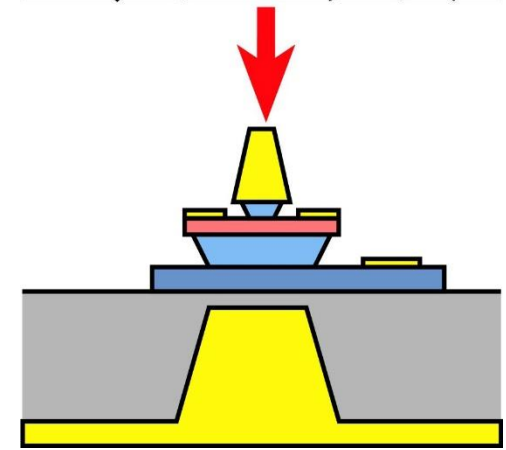
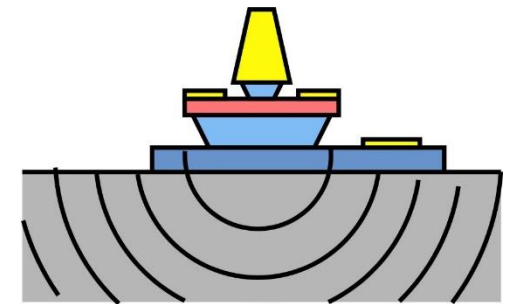
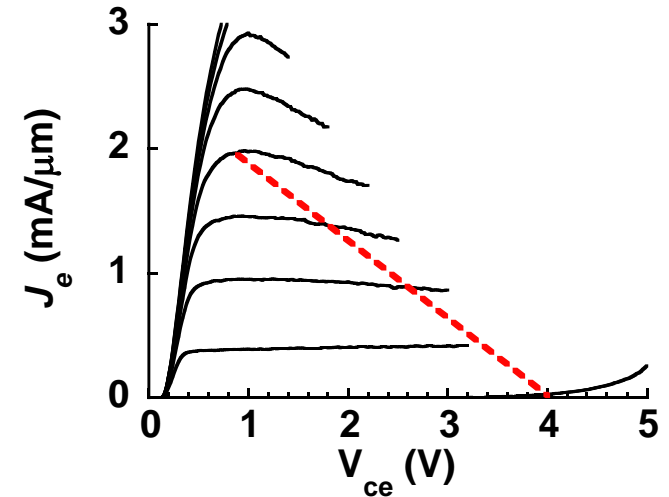
GaN HEMTs:

much higher voltage
100+ GHz: large multi-finger FETs not feasible
Need high current to exploit high voltage.

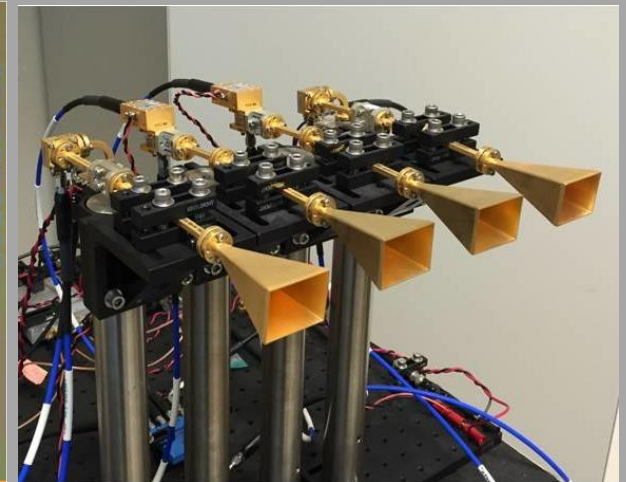
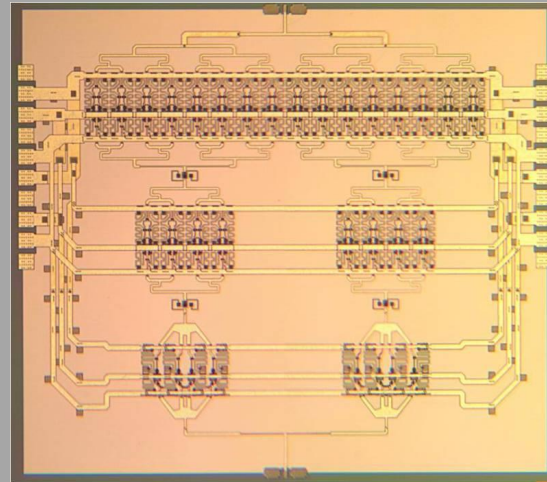
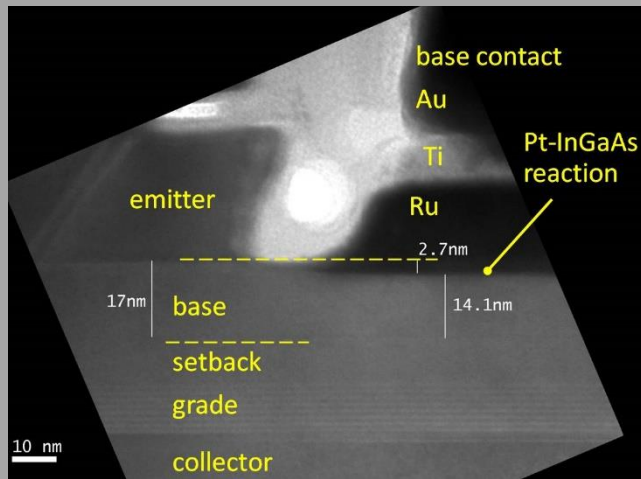
Example:

2mA/μm, 100 μm max gate width, 50 Volts
200mA maximum current
50 Volts/200mA = 250 Ω load → unrealizable.

Need more mA/μm or longer fingers



50-500GHz Wireless

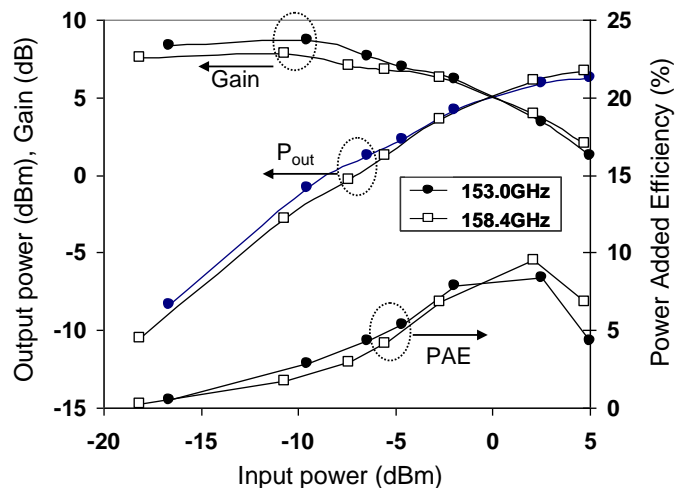
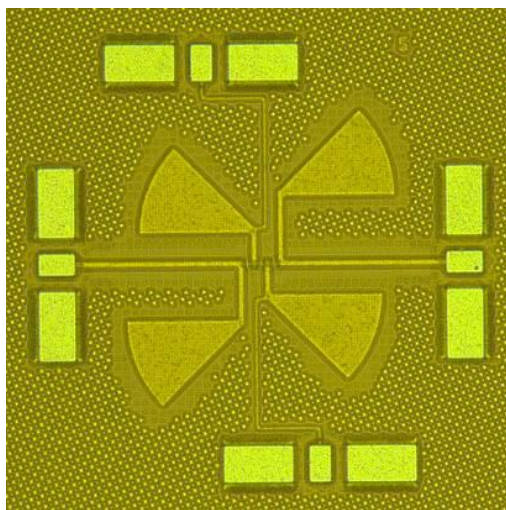
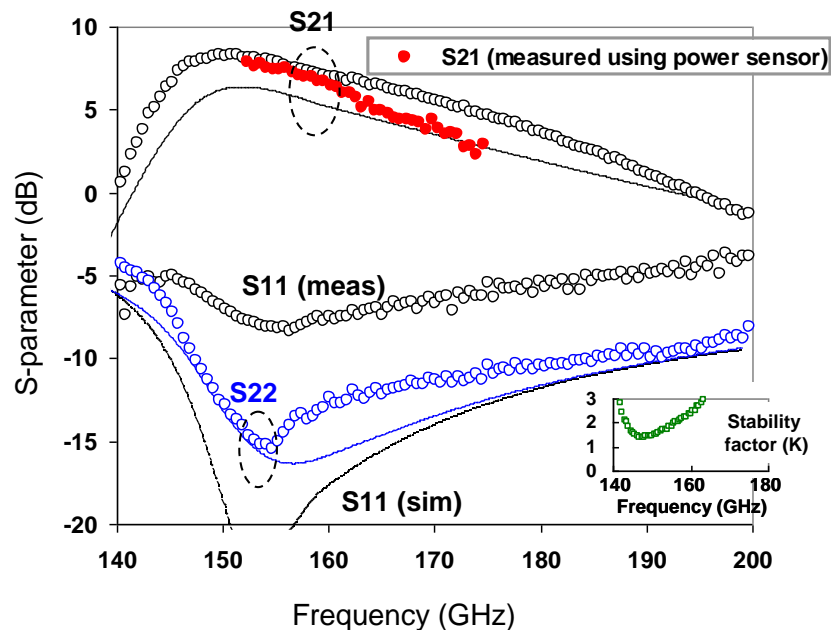
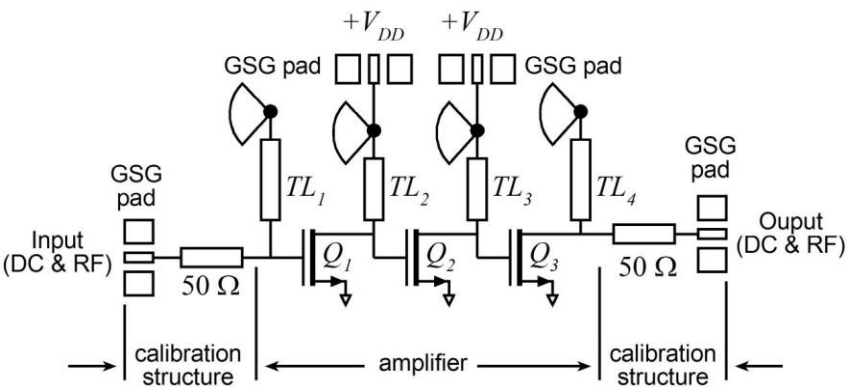


**IC example:
150 GHz
CMOS amplifier**

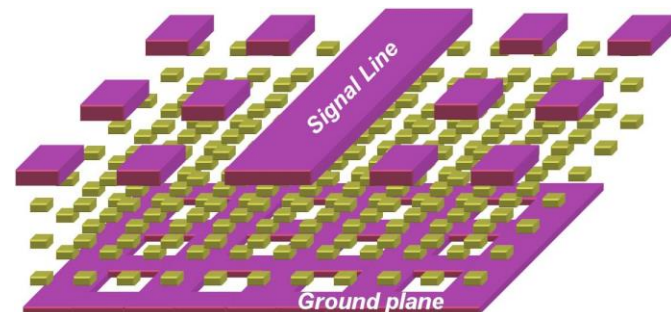
3-stage 150-GHz Amplifier; IBM 65 nm CMOS

Acknowledgement:
IBM

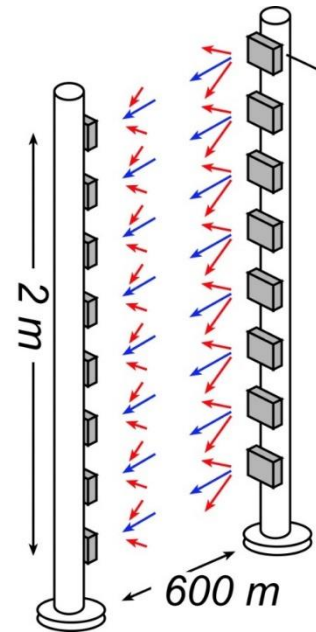
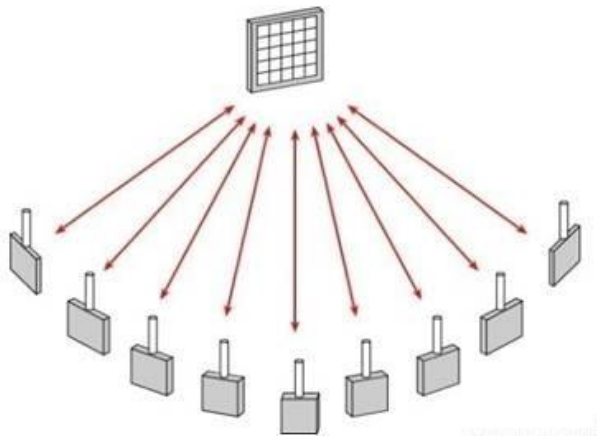
M. Seo, B. Jagannathan, J. Pekarik, M. Rodwell, IEEE JSSCC, Dec. 2009



Dummy-prefilled microstrip lines



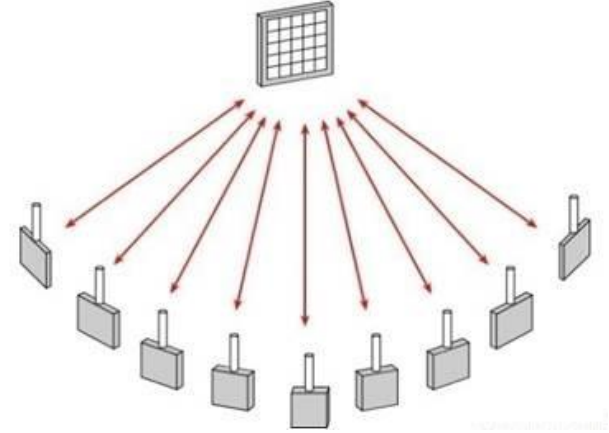
IC example: 140 GHz spatial multiplexing



Massive Spatial Multiplexing

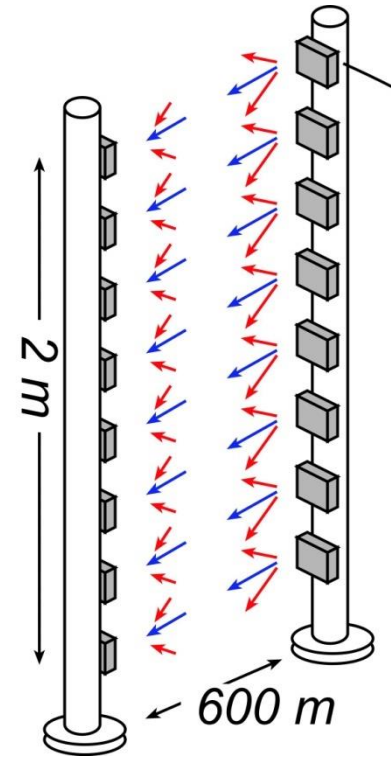
Two applications:

Spatially multiplexed networks
multiple independent beams
carrying independent data
→ spectral re-use for massive capacity



mm-wave line-of-sight MIMO
spatial multiplexing
for increased capacity

These use similar signal processing hardware



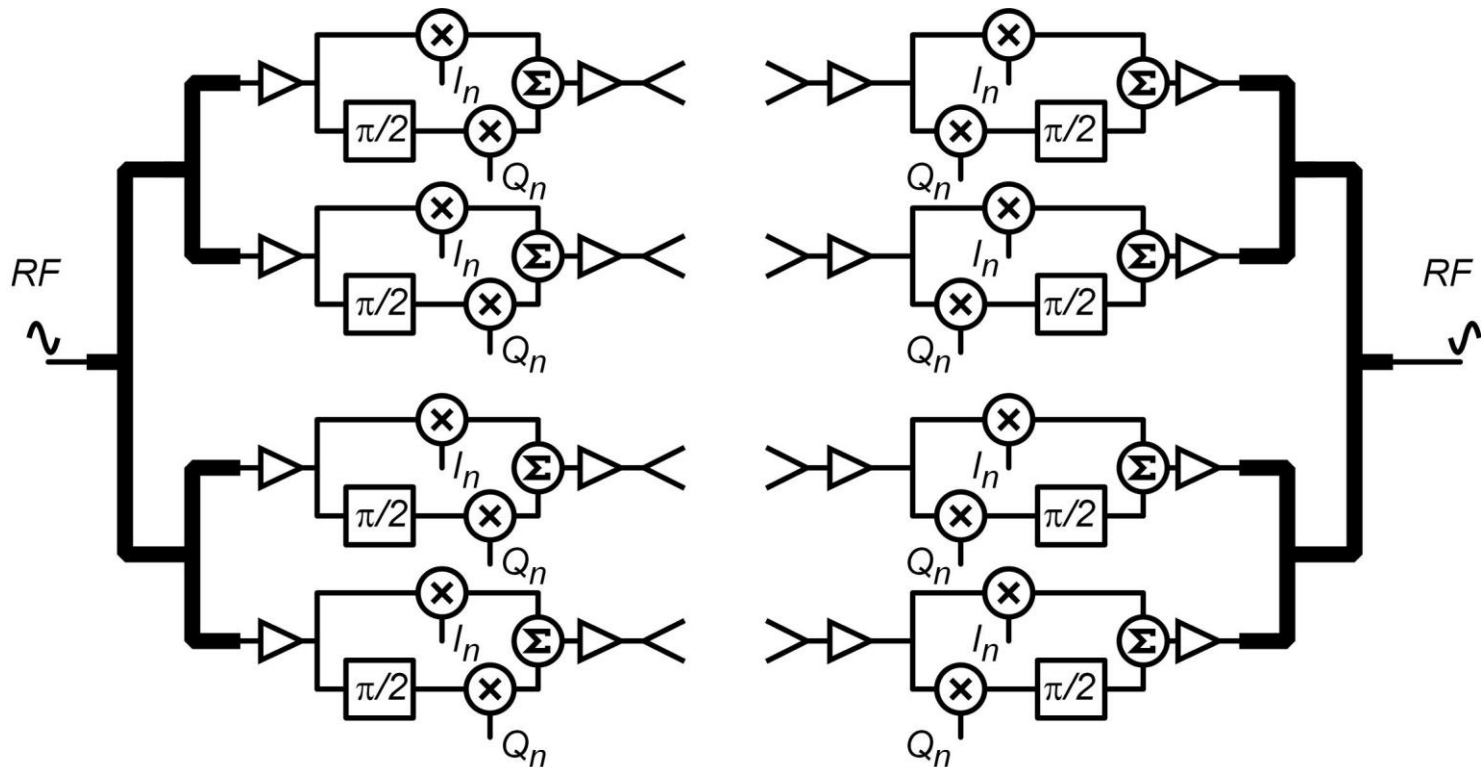
Arrays for **single**-beam links

Single-beam arrays:

steerable, high gain, for mm-wave links.

Simple hardware:

one RF port for IC, one phase-shifter for each element



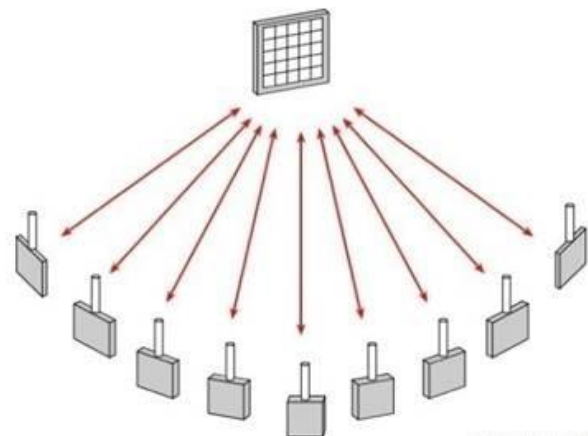
Multi-beam links: hardware design

multiple independent beams

each carrying different data

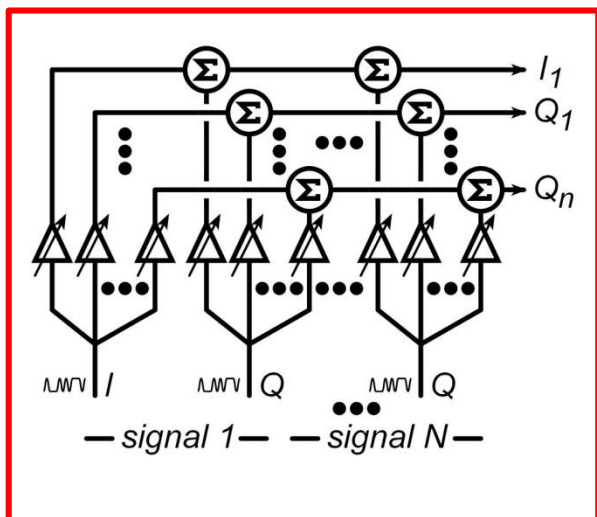
each independently aimed

beams = # array elements

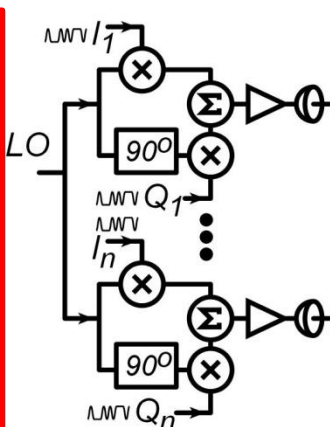


Hardware: multi-beam phased array ICs

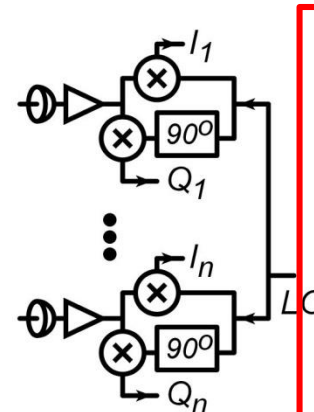
transmit matrix



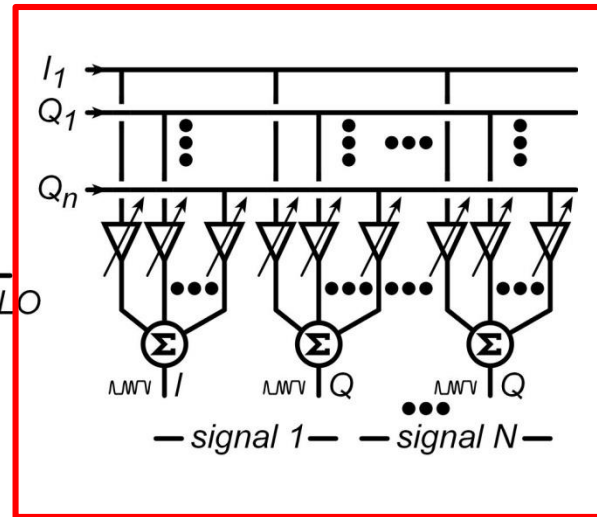
trx array



rcvr array



receive matrix



Multi-Beam Links: Analog Beamformer Matrix

I/Q matrix at baseband

varying coefficients

→ track/aim beams

Designs: March tapeout

GF (ex IBM) 45nm SOI

16 beams: 32 x 32 matrix

1024 matrix elements

area: 2.25 mm²

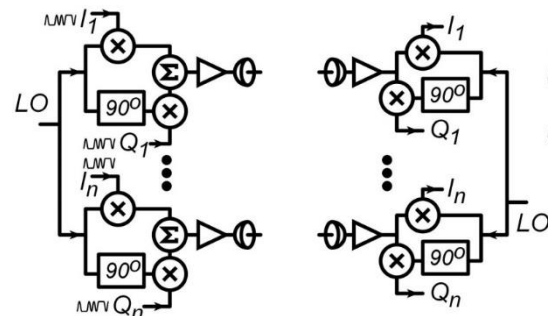
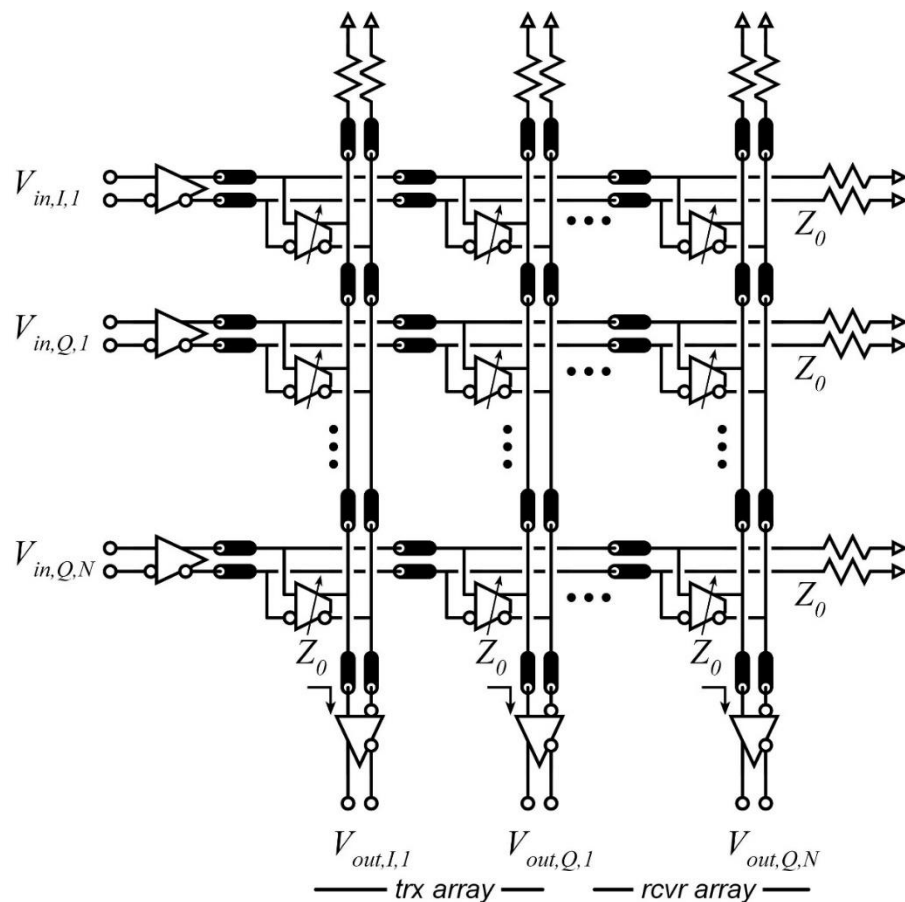
power: 2.25W

bandwidth: ~5 GHz ?

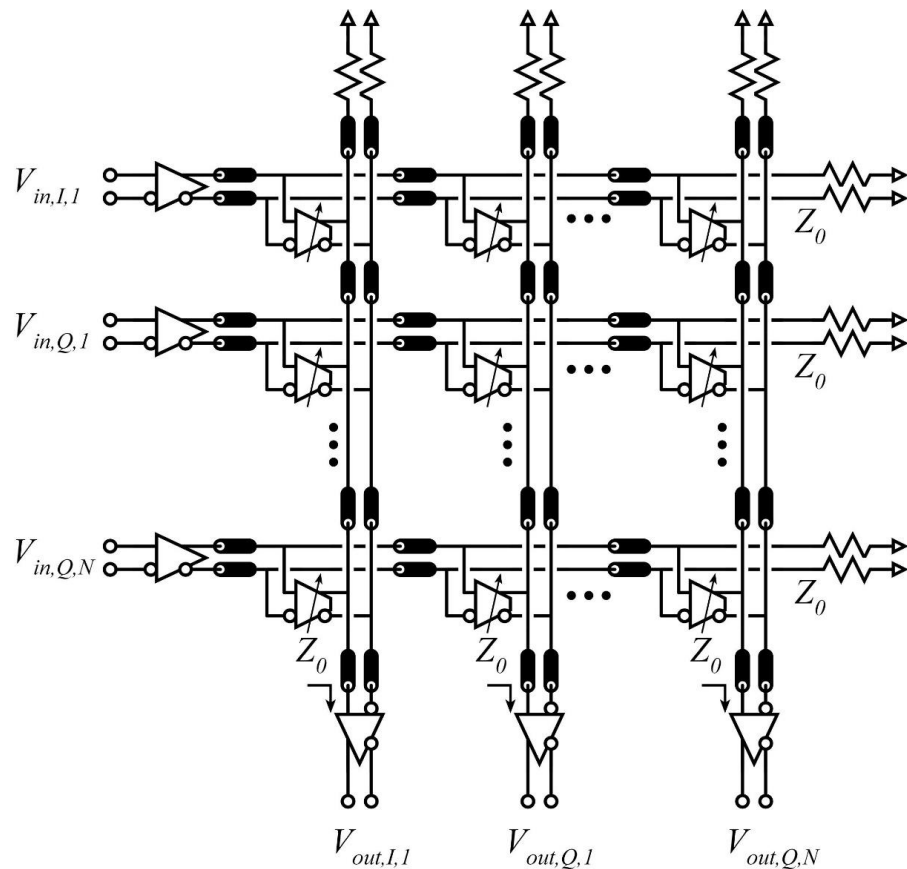
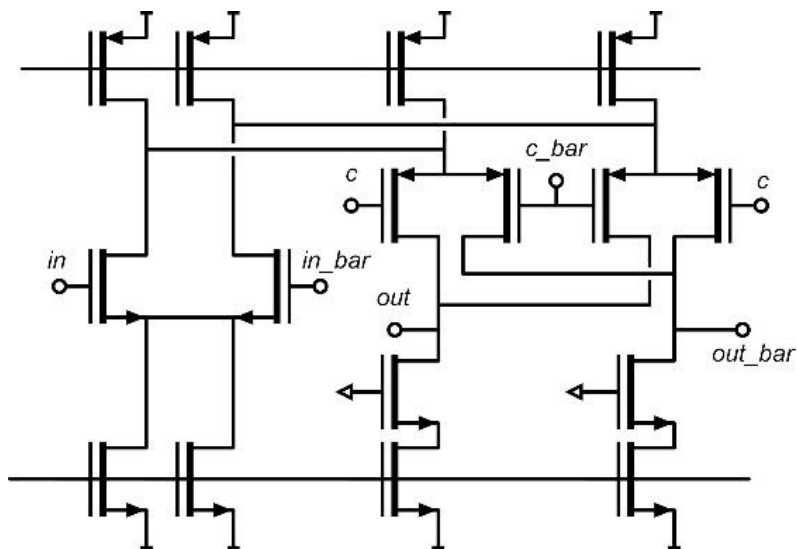
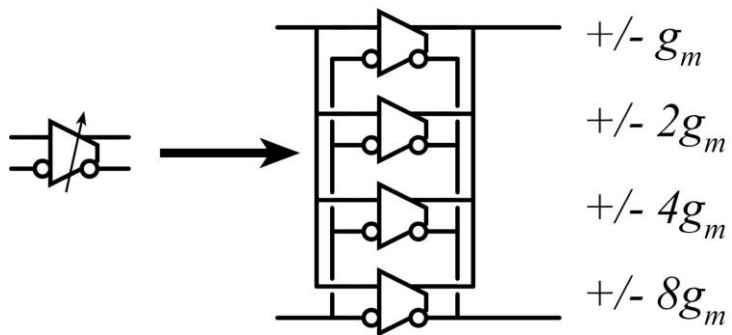
aggregate ~160 Gb/s.

Also for tapeout

140 GHz front-ends for these



Multi-Beam Links: Analog Beamformer Matrix



Multi-Beam Links: Analog Beamformer Matrix

I/Q matrix at baseband

varying coefficients

→ track/aim beams

Designs: March tapeout

GF (ex IBM) 45nm SOI

16 beams: 32 x 32 matrix

1024 matrix elements

area: 2.25 mm²

power: 2.25 W

bandwidth: ~5 GHz ?

aggregate ~160 Gb/s.

Also for tapeout

140 GHz front-ends for these

later: RF for 38GHz, 60 GHz



cell

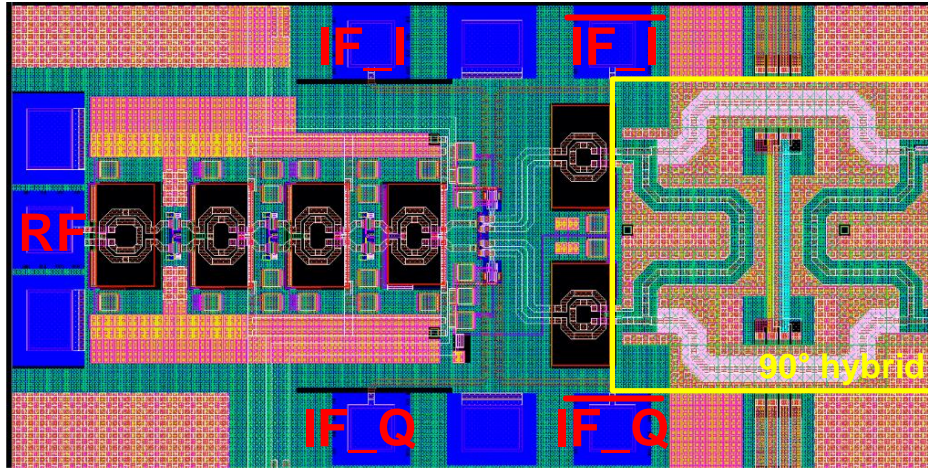


switched g_m block

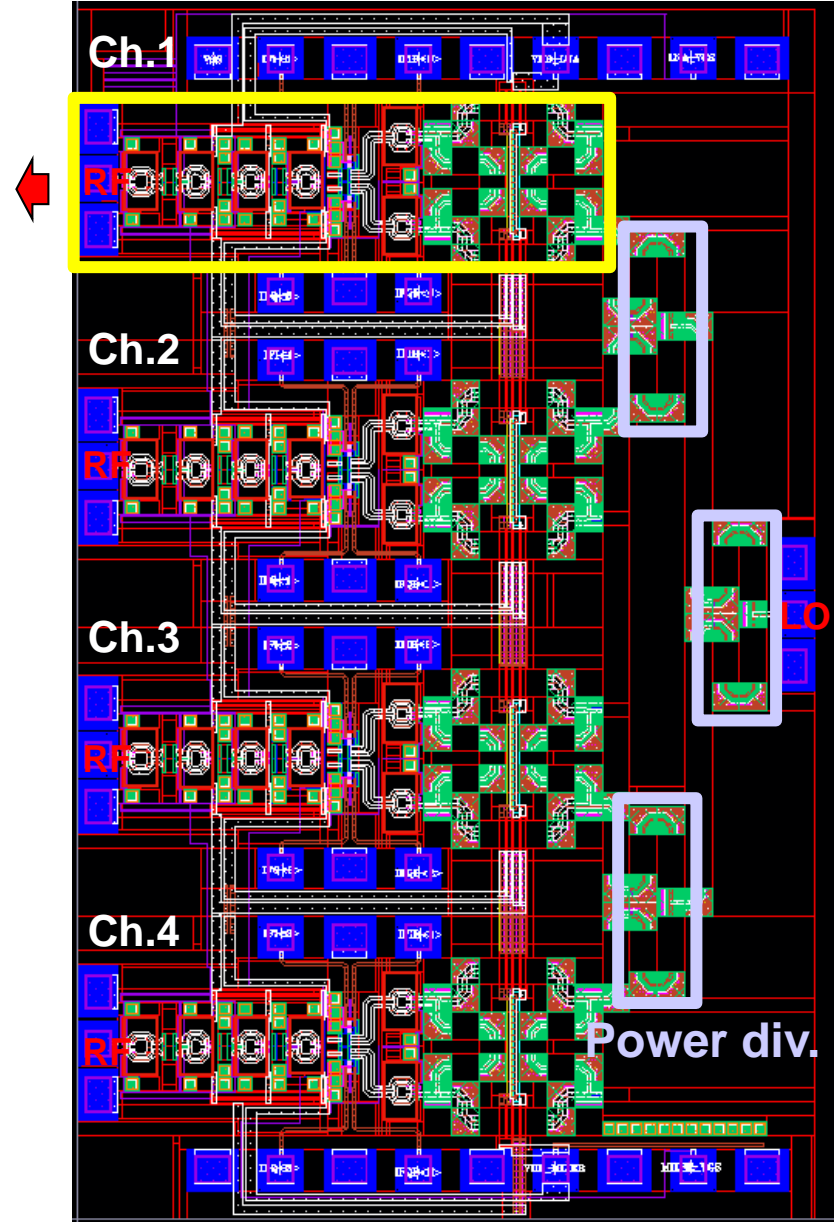
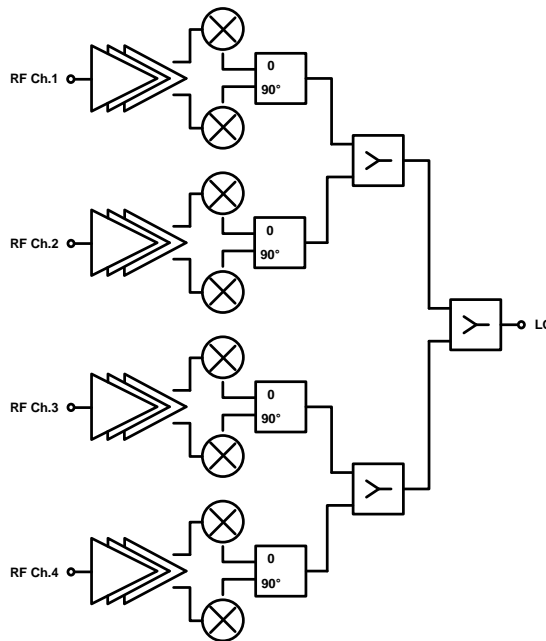
array

140 GHz MIMO receiver front-end

Size: 1075 x 1760 μm^2



Single-channel layout

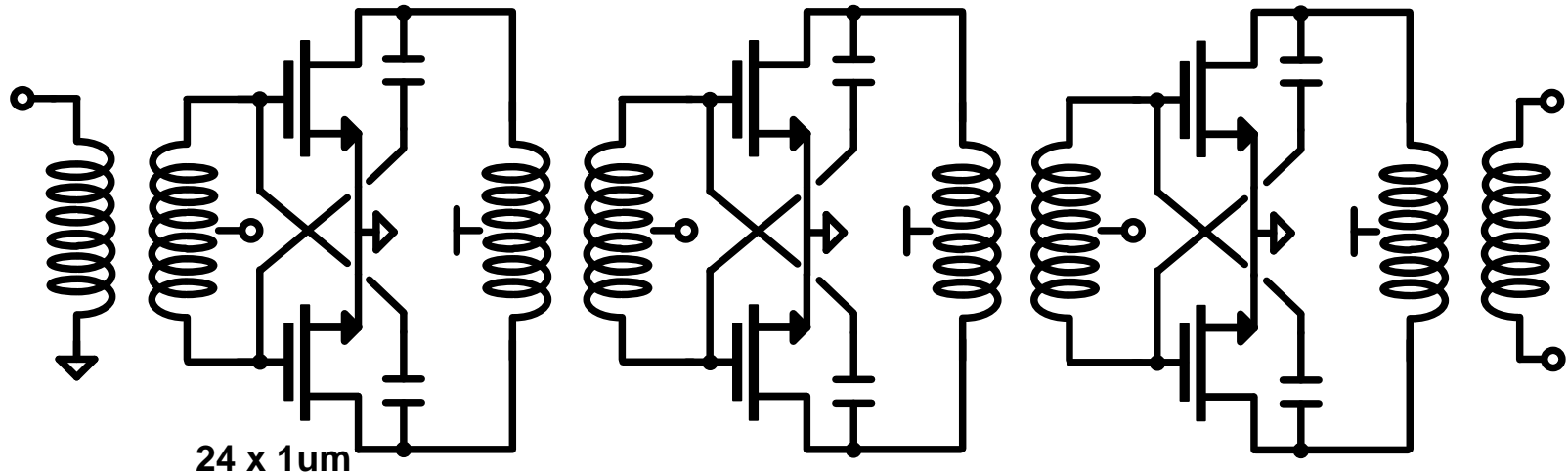


Single-ended vs differential

	Single-ended	Differential
Gain	-	-
Power consumption	Low	High
Design complexity	Low	High (Balun is required)
Isolation (S12) & Stability	Low	High (C_{gd} cancellation)
Power supply (VDD & VSS) immunity	Poor	Good

Power supply immunity is critical → differential structure

Low noise amplifier



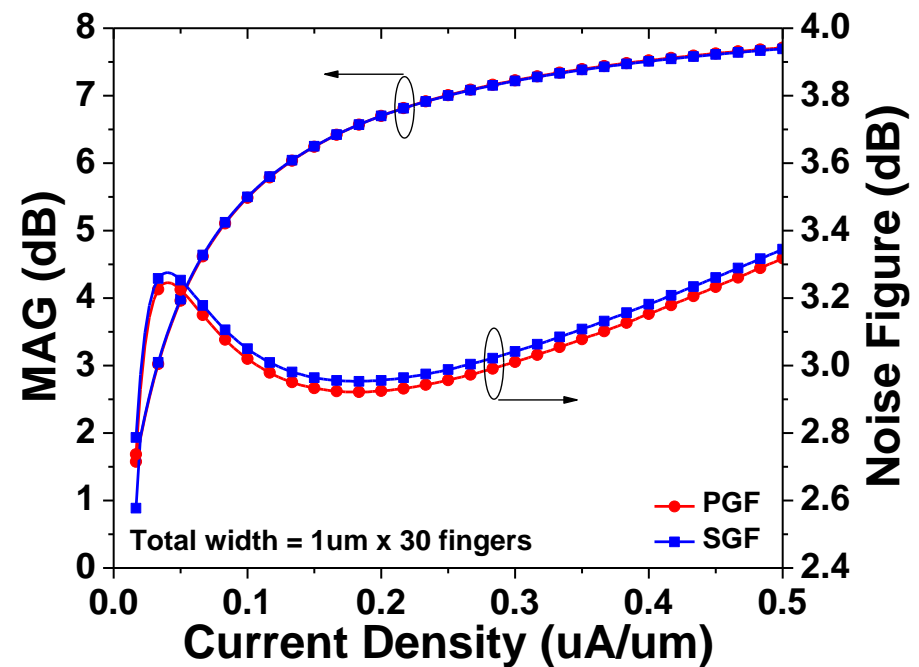
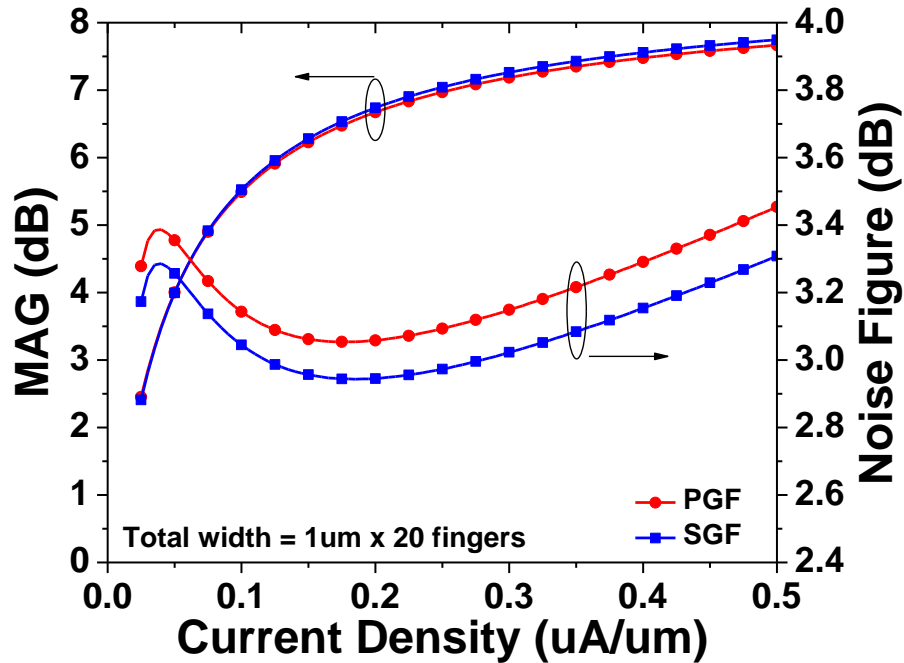
LNA design:

3-stage differential CS amplifier

C_{gd} cancellation

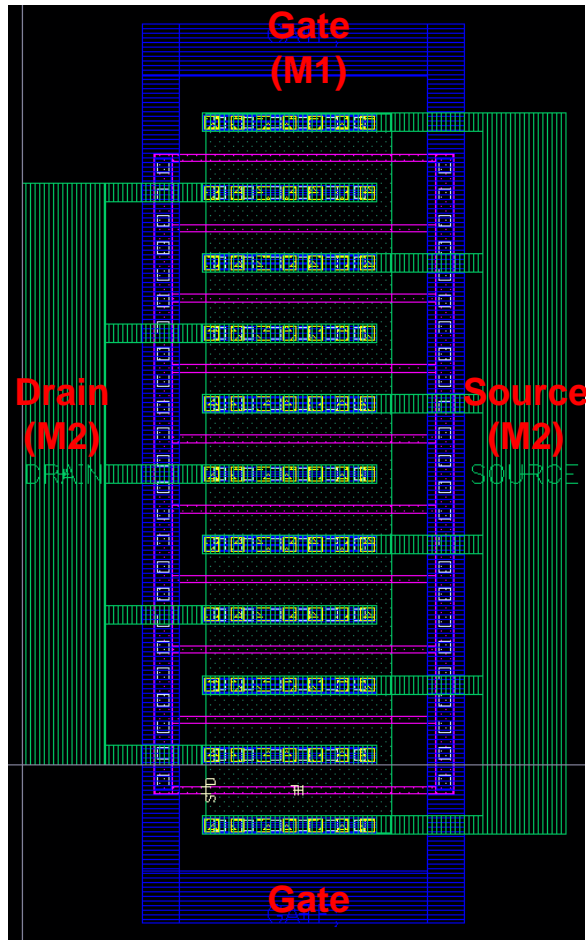
Transformers for matching networks and sing.-to-diff.

SGF vs PGF

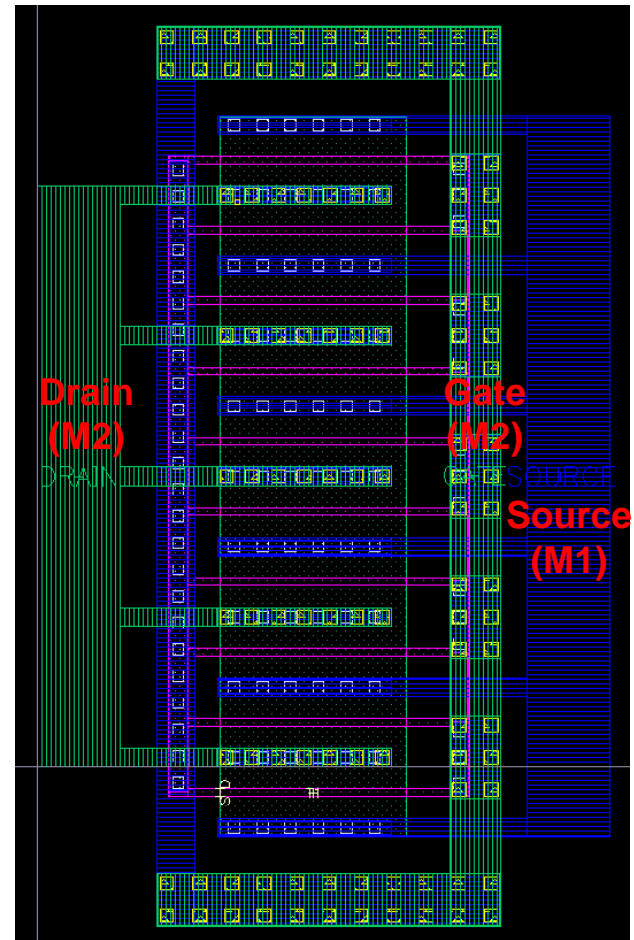


**Simulation results includes BSIM model and PEX results
(PEX → capacitance and resistance due to PC, CA and M1)**

FET footprint

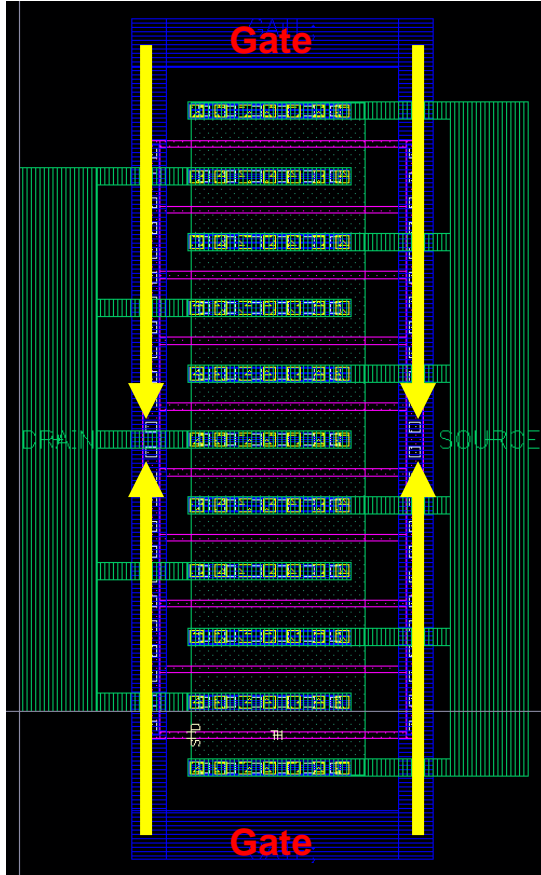


Series gate feeding



Parallel gate feeding

FET footprint - PGF

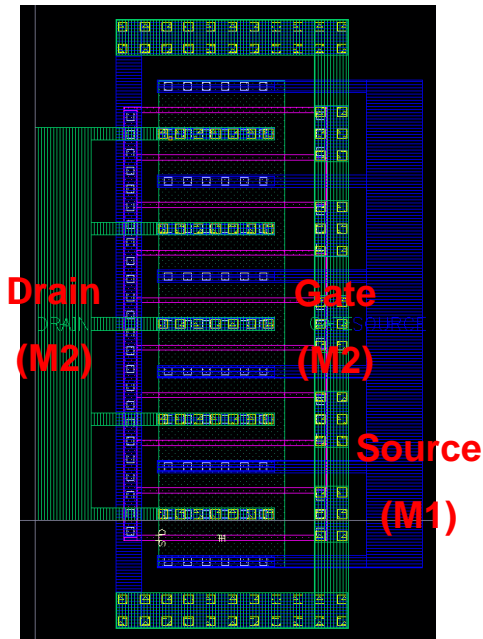


SGF

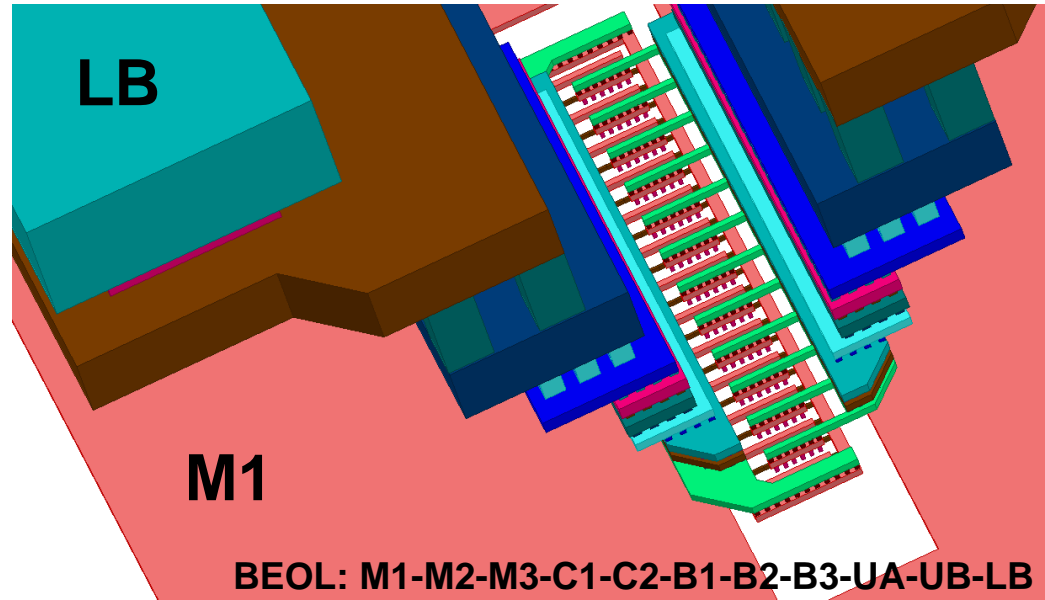
PGF

- PGF and SGF have similar performances (MSG, NF)
- SGF is hard to extract the inductance of the gate feeding line
- Source can directly connect to ground (M1 is the ground plane)

FET modeling

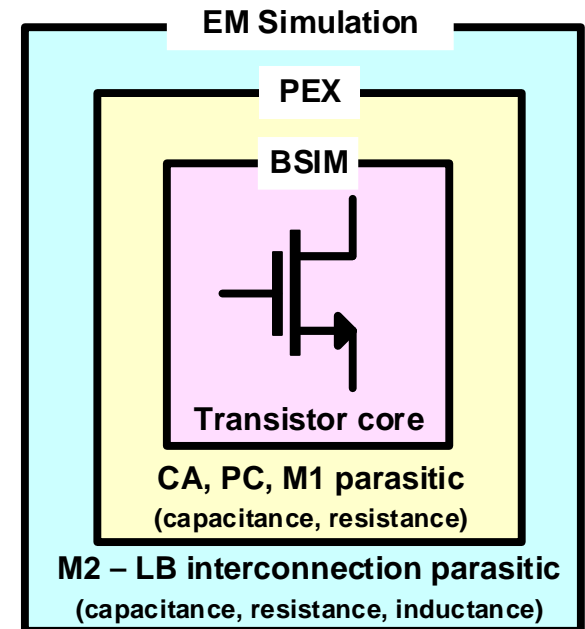


Parallel Gate Feeding

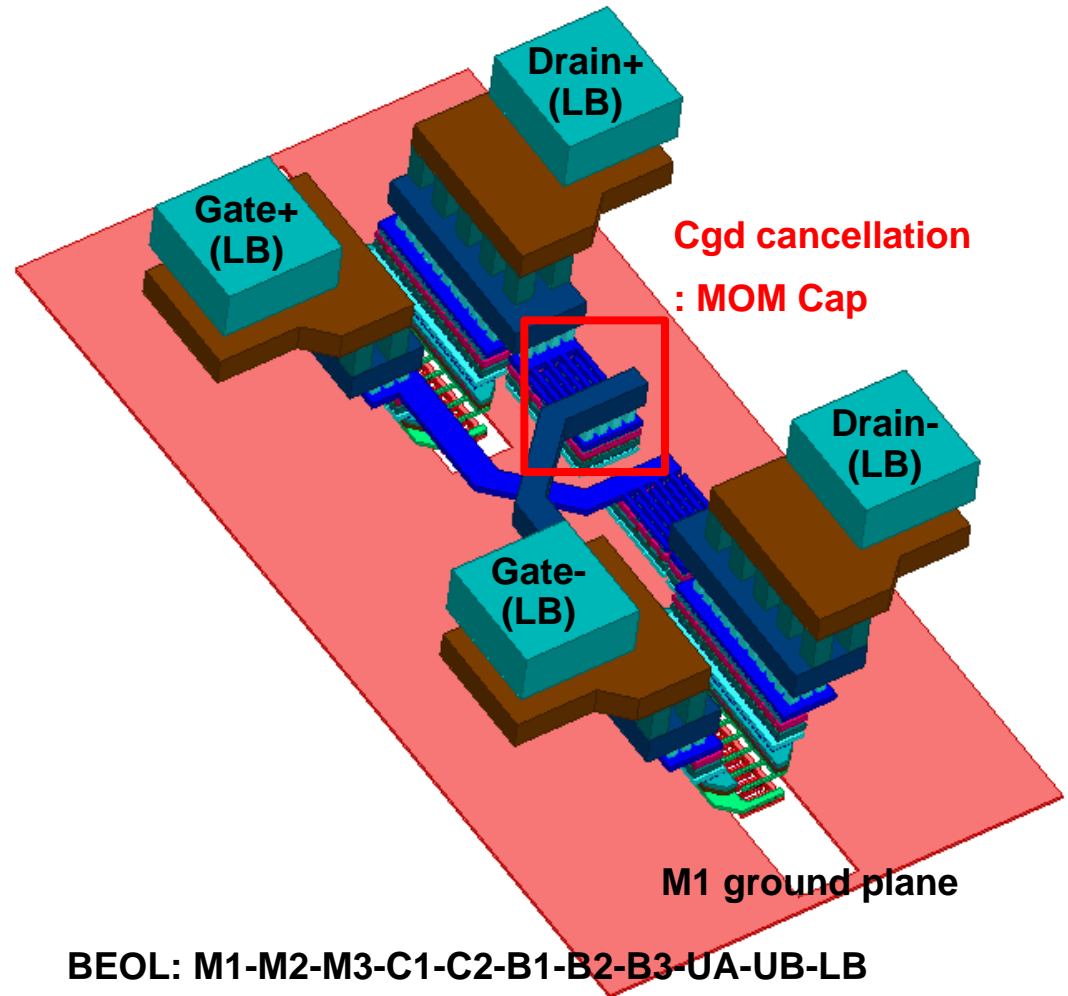
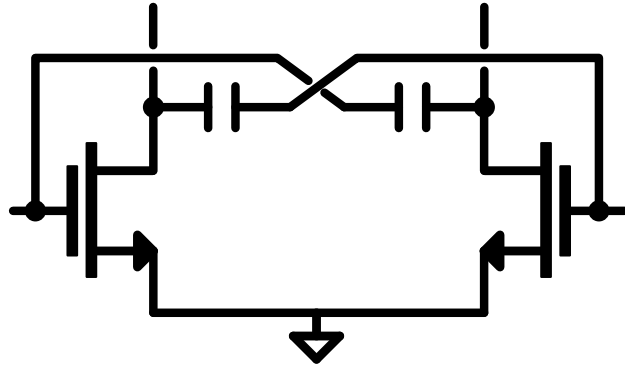


BEOL: M1-M2-M3-C1-C2-B1-B2-B3-UA-UB-LB

**Transistor modeling:
BSIM + PEX + EM simulation
(BSIM & PEX from the foundry)**

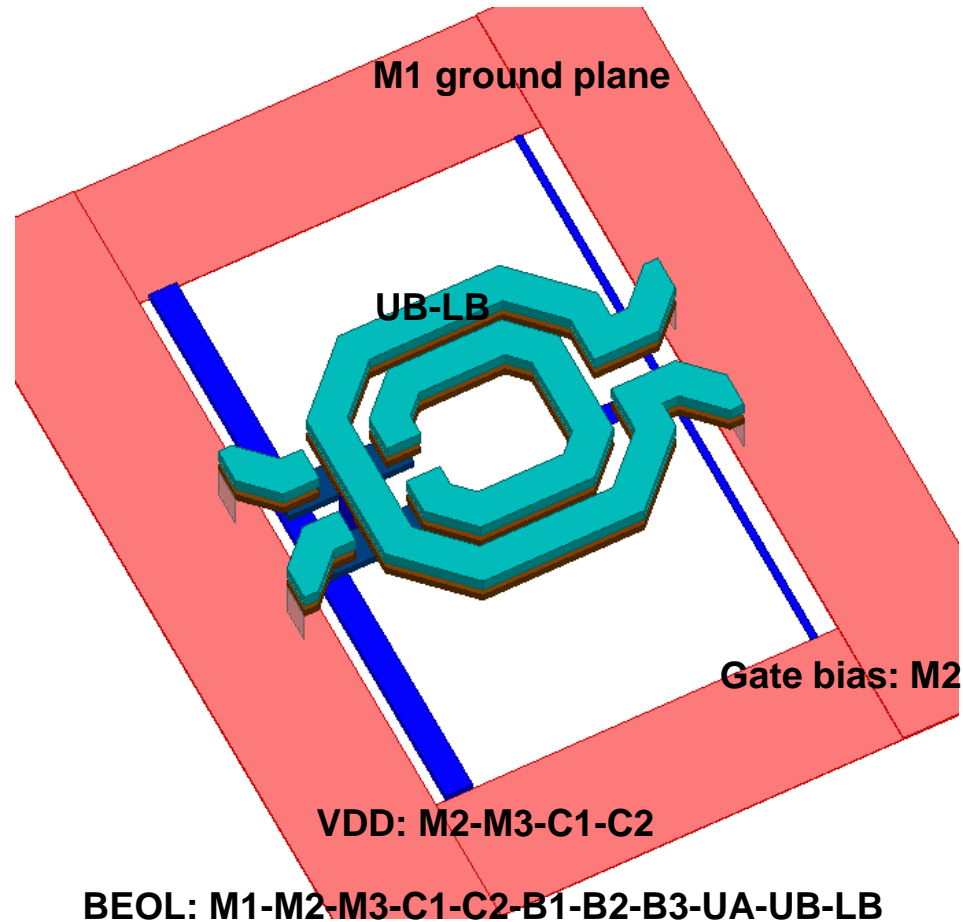


FET differential pair layout



C_{gd} cancellation – better isolation & gain

Matching networks

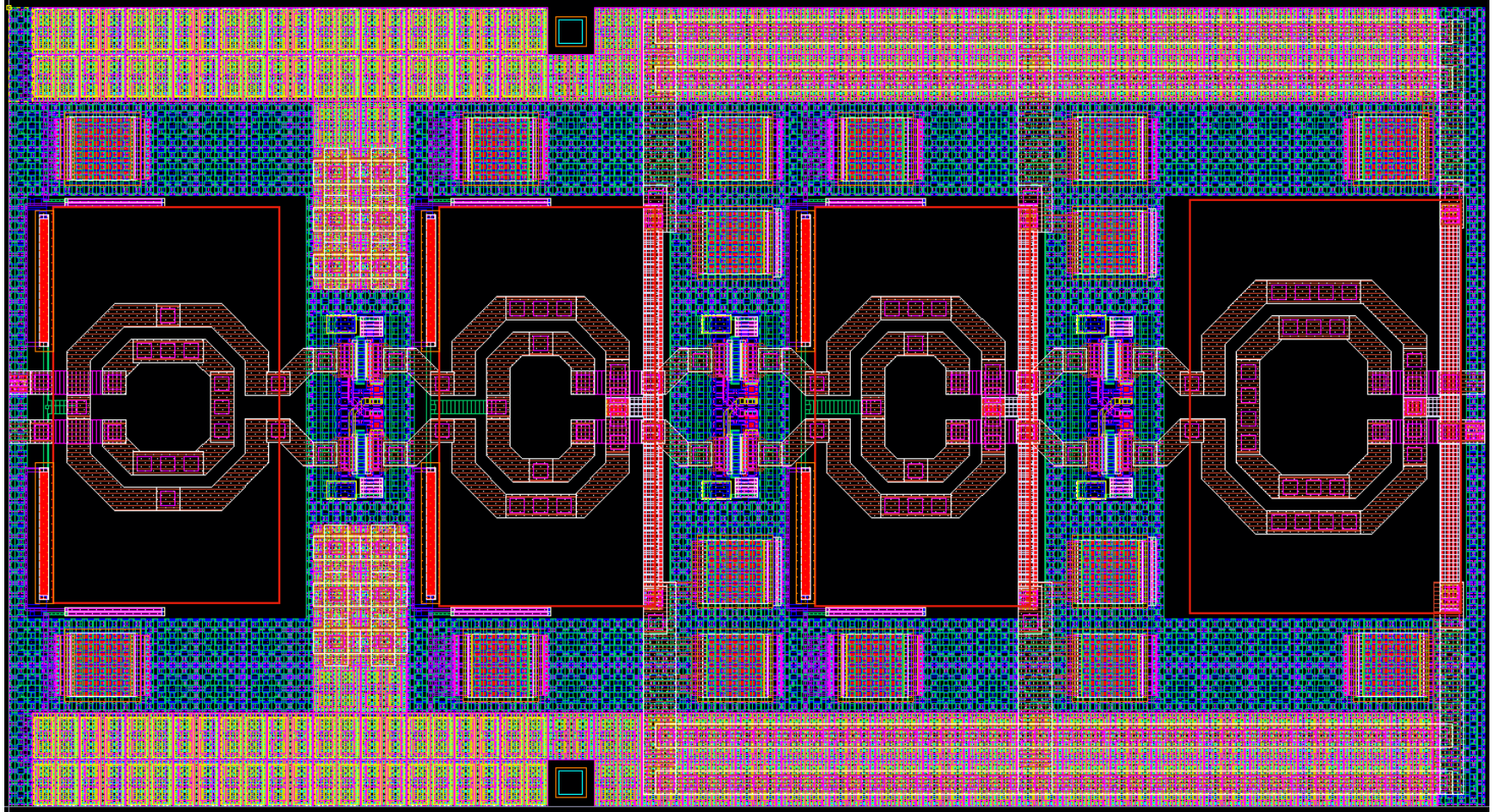


For matching:

Optimize transistor size & transformer diameter

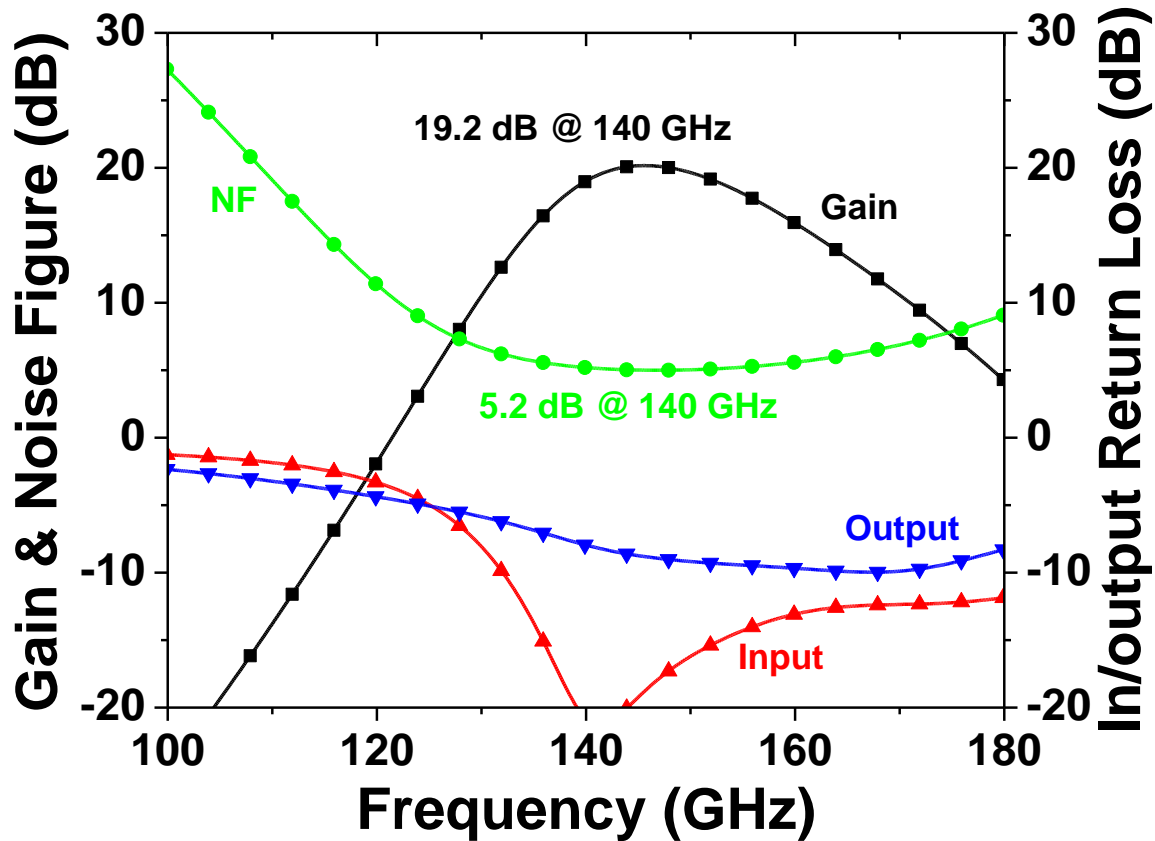
Center-tapped transformer for DC biasing (VDD, VGS)

LNA layout



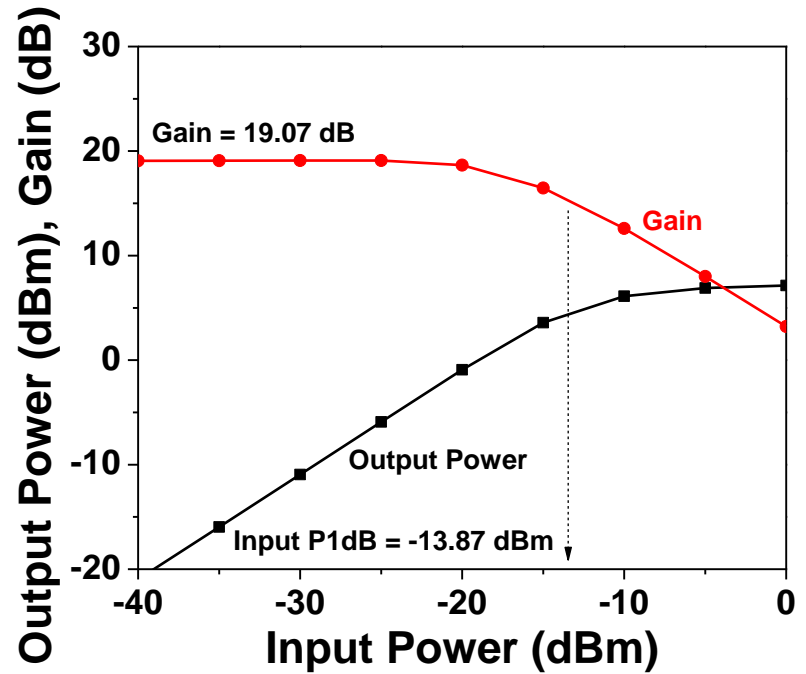
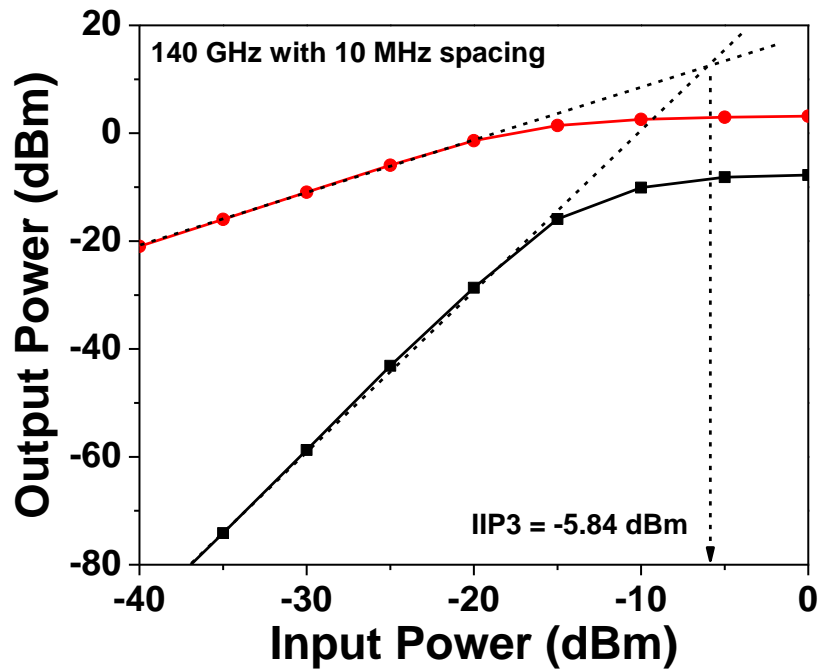
Size: 315 x 170 μm^2

Gain & NF



Gain 19.2 dB (peak gain 20 dB @ 145 GHz)
NF: 5.2 dB

Linearity

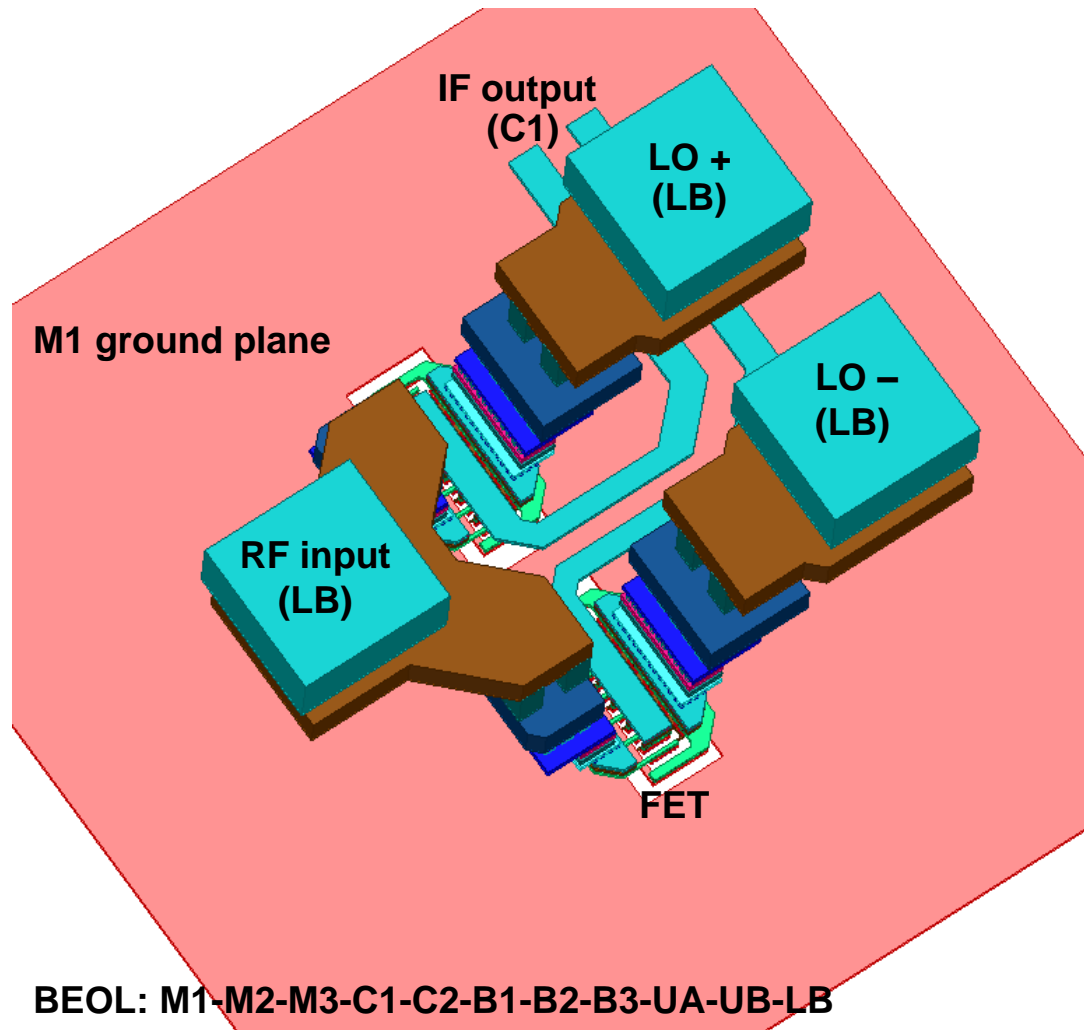


IIP3: -5.84 dBm, Input P1dB: -13.87 dBm

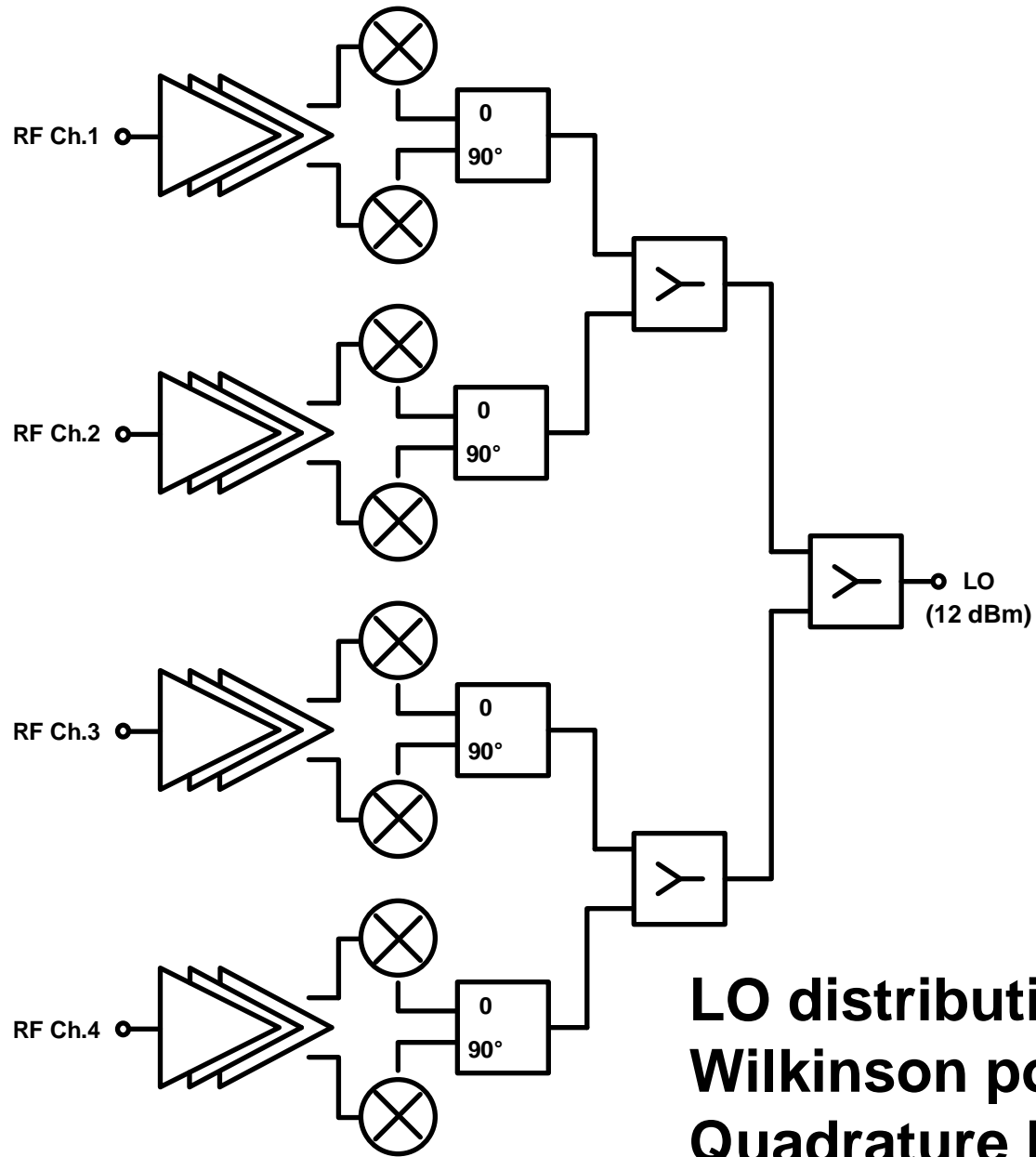
Summary - LNA

Gain	19.2 dB (Peak 20 dB @ 145 GHz)
NF	5.2 dB
IIP3	-5.8 dBm
Input P1dB	-13.87 dBm
Power consumption	41 mA @ 1 V
Size	315 x 170 μm^2

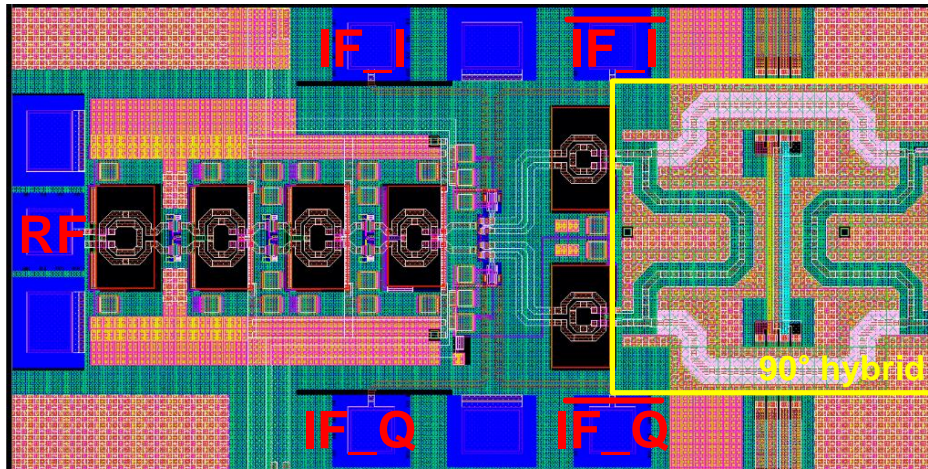
Mixer core layout



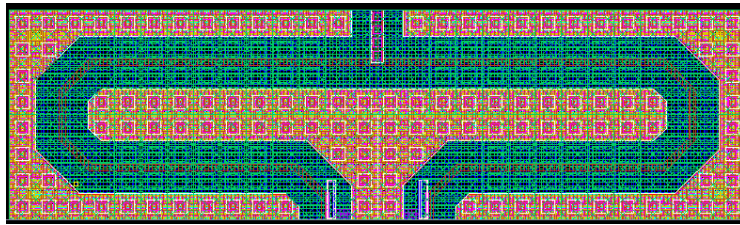
Four-channel receiver



Layout

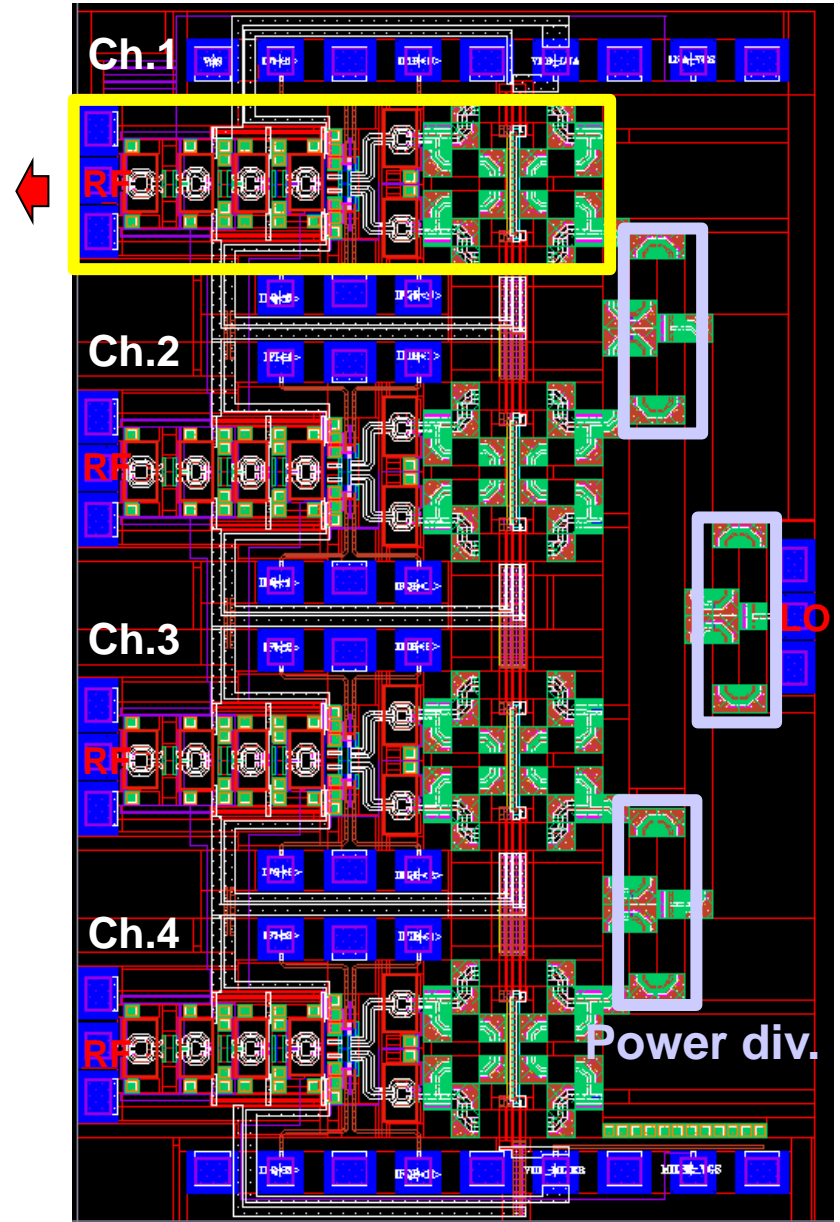


Single-channel layout

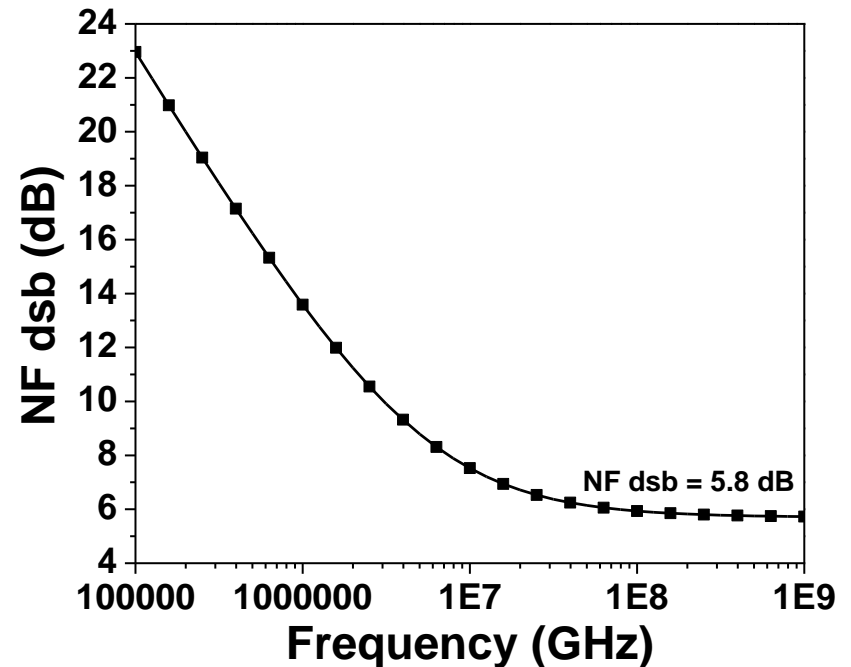
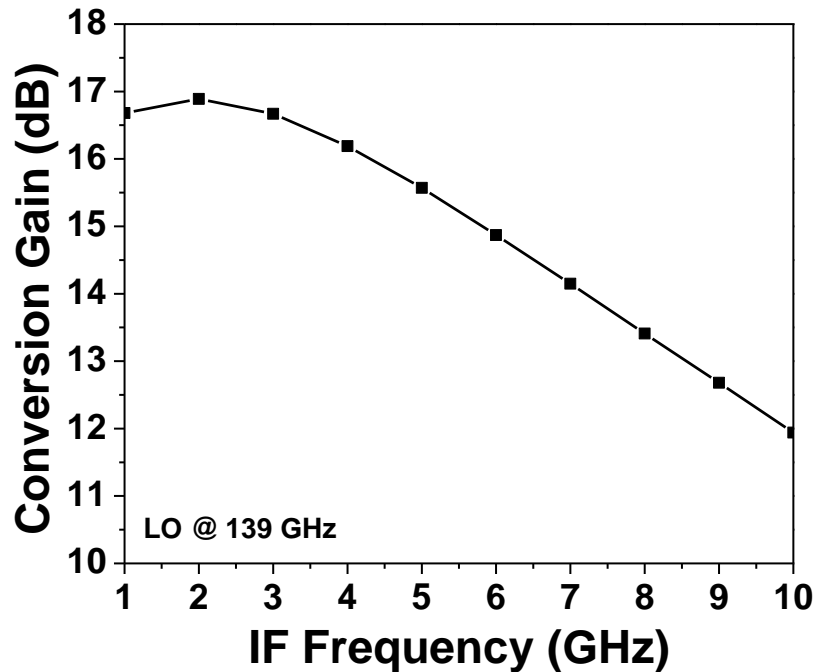


Wilkinson power divider

Size: 1075 x 1760 μm^2

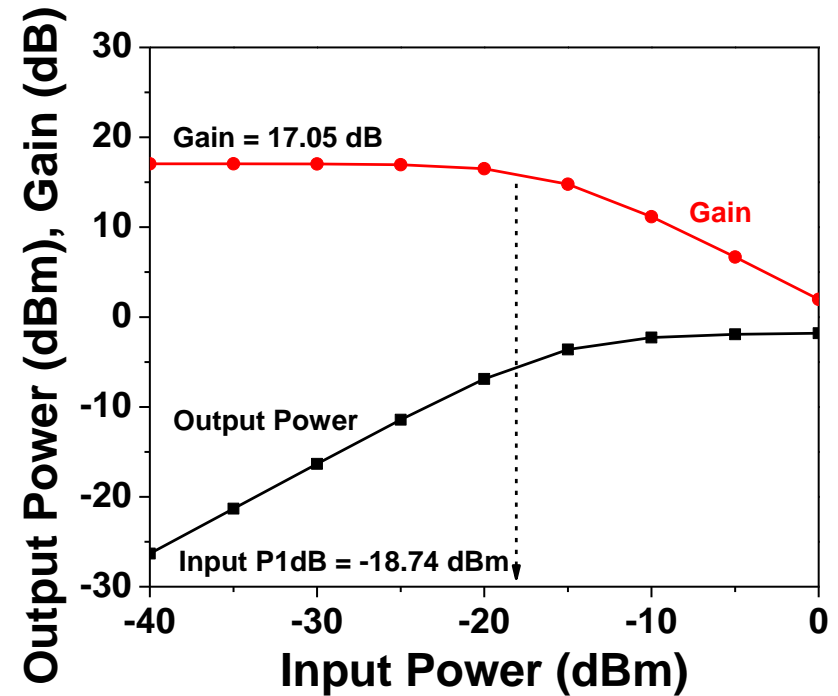
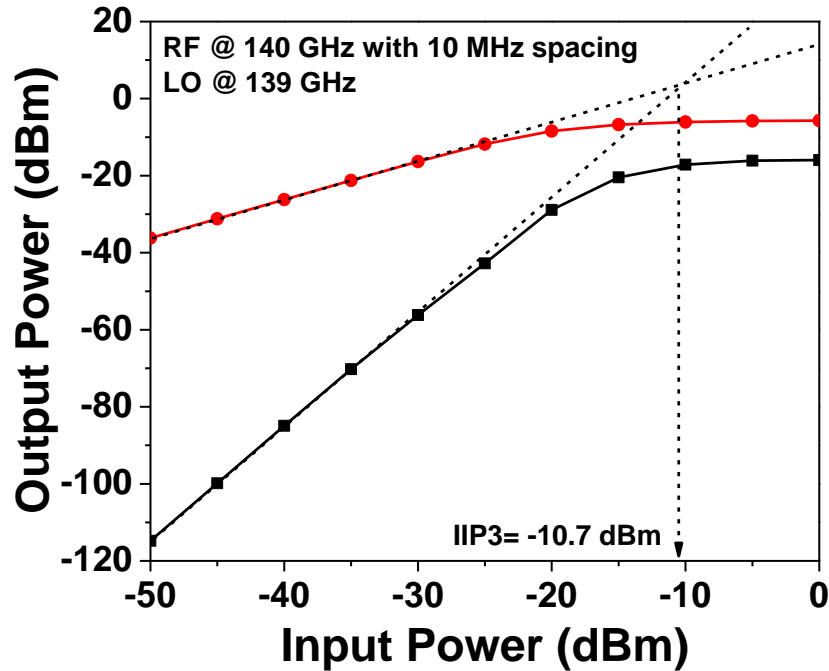


Conversion gain & NF (single-channel)



Gain 17 dB (single-channel IF_I output)
NF : 5.8 dB (dsb)

Linearity (single-channel)



IIP3: -10.7 dBm, Input P1dB: -18.74 dBm

Summary - receiver

Gain	17 dB (Single-channel IF_I output)
NF	5.8 dB
IIP3	-10.7 dBm
Input P1dB	-18.7 dBm
Power consumption	41 mA (LNA) + 2 mA (I/Q mixer) + 14 mA (IF-I/Q buffers) @ 1 V (Single-channel)
Size	1075 x 1760 μm^2

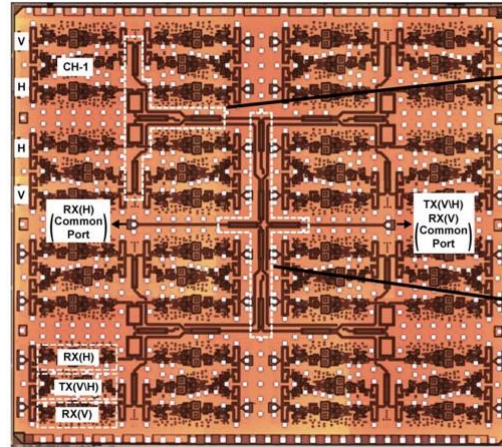
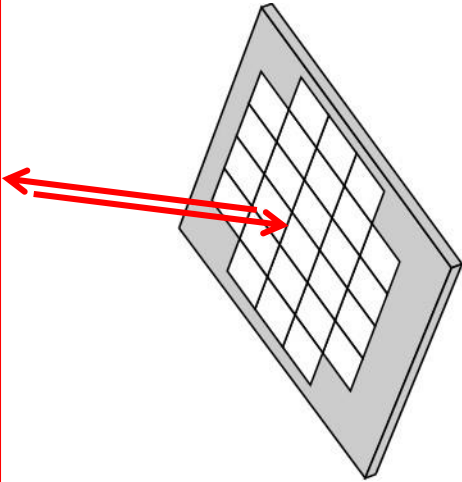
IC example:

94 GHz

low-power-array

Millimeter-wave imaging

10,000-pixel, 94GHz imaging array → 10,000 elements



Golcuk: Trans MTT, Aug 2014

Demonstrated:

SiGe (UCSD/Rebeiz)

~1.3kW: 10,000 elements

Lower-power designs:

InP, CMOS, SiGe

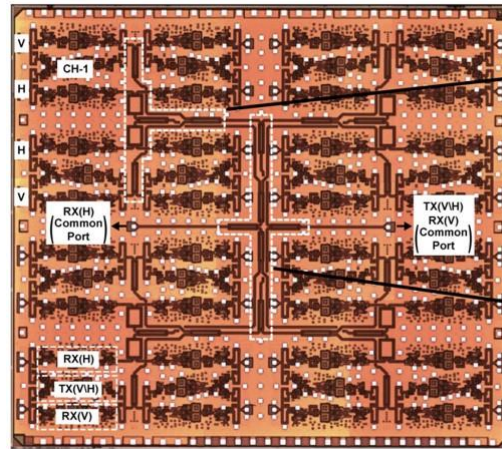
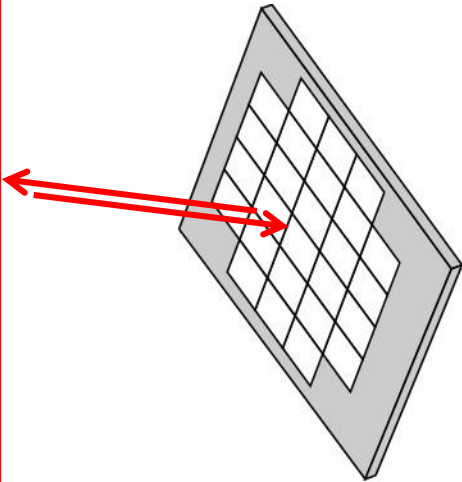
(UCSB, UCSD, Virginia Poly.)



System concept: Bruce Wallace DARPA. 1st ICs (SiGe) Rebeiz, UCSD.

Millimeter-wave imaging

10,000-pixel, 94GHz imaging array → 10,000 elements



Golcuk: Trans MTT, Aug 2014

Demonstrated:

SiGe (UCSD/Rebeiz)

~1.3kW: 10,000 elements

Lower-power designs:

InP, CMOS, SiGe

(UCSB, UCSD, Virginia Poly.)

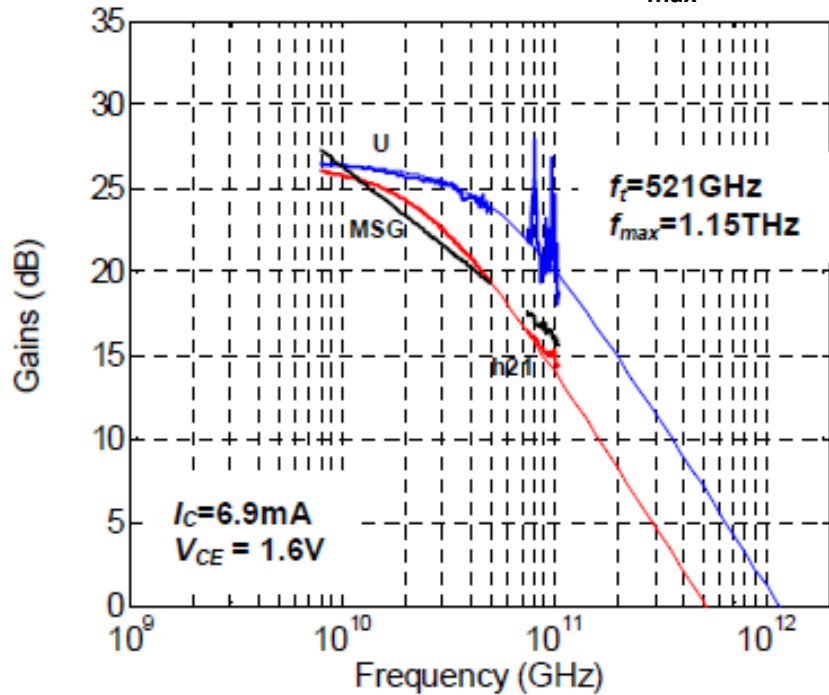
100 pixel × 100 pixel image → 10,000 array elements.

~130 mW DC power per element → 1.3 kW system power requirement.

Problem: required size and weight of heat sink.

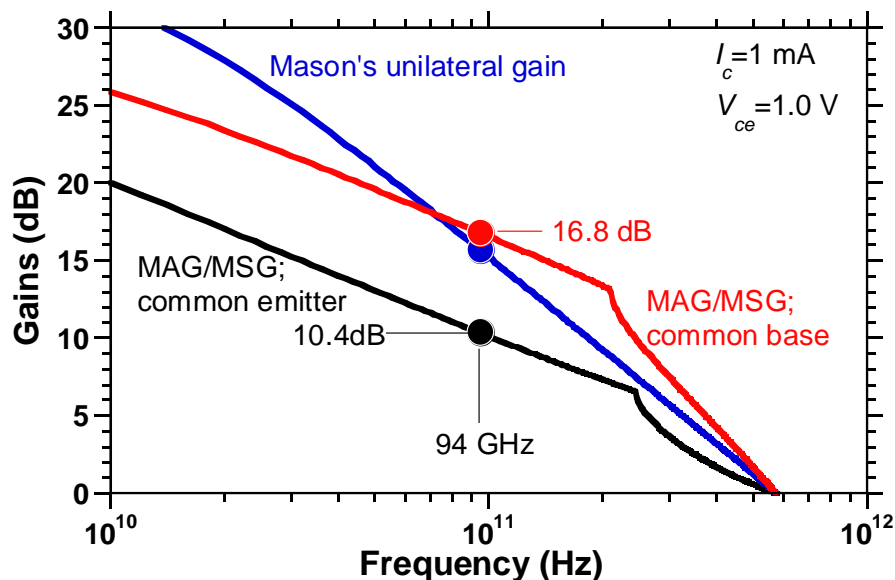
94 GHz low-power IC design: transistors

Teledyne: 130nm InP HBT: high- f_{max} bias



Teledyne: M. Urteaga *et al*: 2011 DRC

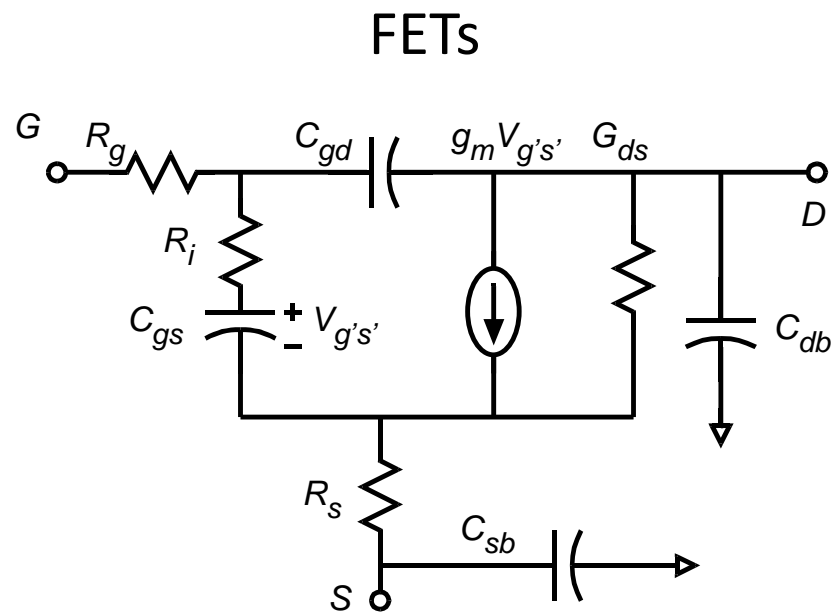
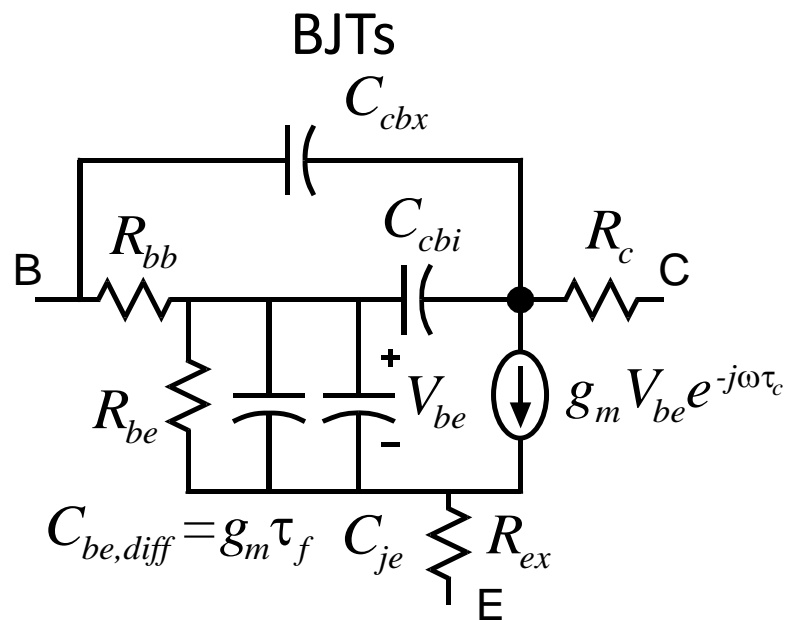
Teledyne: 130nm InP HBT: low-power bias



130nm \times 3 μ m emitter

At 1mW dissipation, ~ 17 dB gain is feasible \rightarrow low power ICs.

94 GHz low-power IC design: transistors



RF: transistor must be sized to make impedance - matching possible

$$\text{FETs \& BJT}s : Z_{in} \approx R_{g/BB} + (j\omega C_{gs/be})^{-1} \approx (K / g_m) + (f_\tau / jf)(1 / g_m) \propto 1 / g_m$$

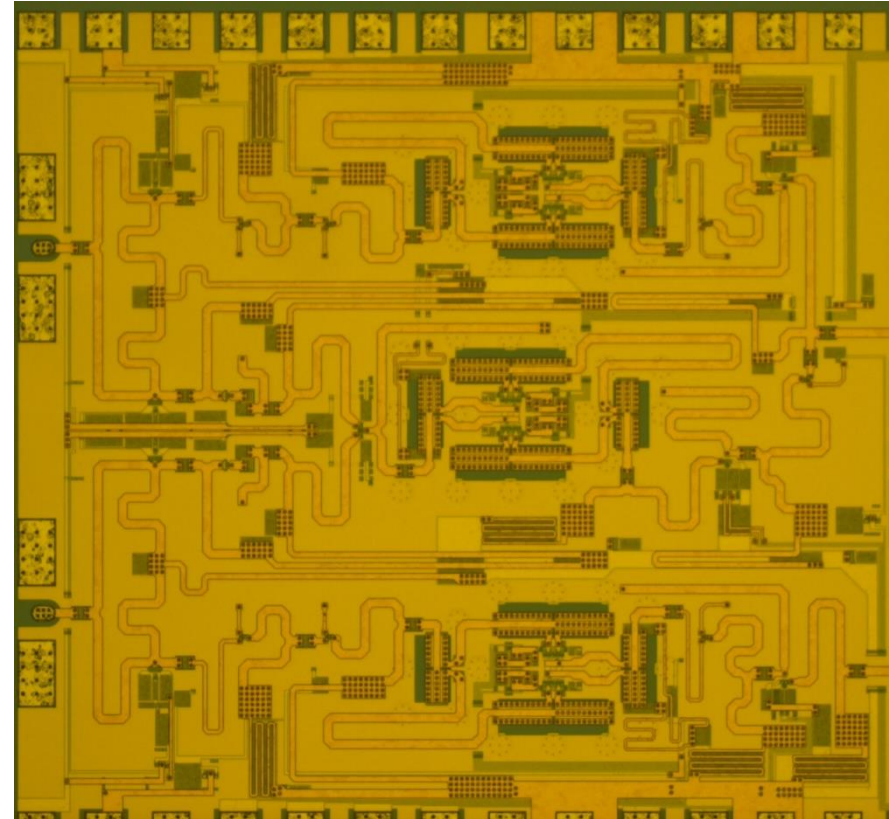
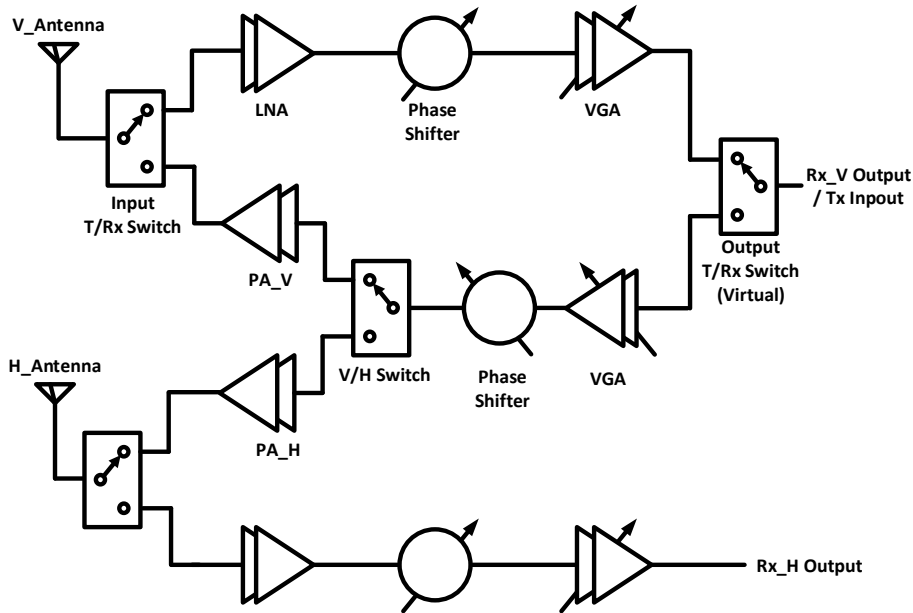
$$\text{BJT}s : g_m \cong I_E / 26 \text{ mV.}$$

$$\text{FET}s : g_m \sim I_S / 300 \text{ mV.}$$

→ low - power mm - wave ICs should use BJT

(ignores P_{sat} , IP3 considerations)

Phased array



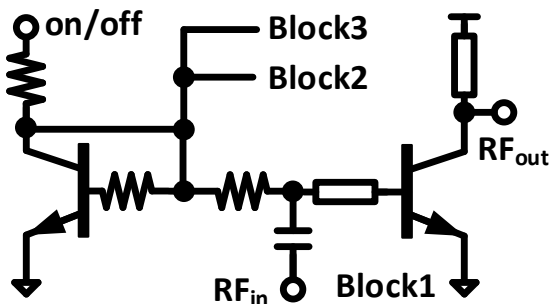
1770 um x 1550 um

IC can transmit on vertical (V) or horizontal (H) polarizations (one at a time)
IC can receive on vertical (V) and horizontal (H) polarizations (simultaneously)
Each mode has phase-shifter, VGA.
Signal distribution on backplane.
InP IC: requires low-speed CMOS digital control IC

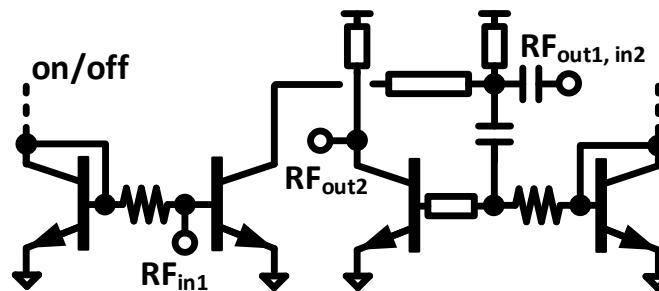
Low-power, low-voltage mm-wave design

Extensive use of current mirrors, translinear techniques

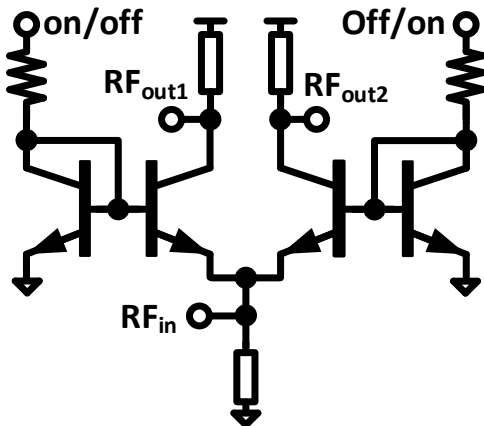
Gain & switching



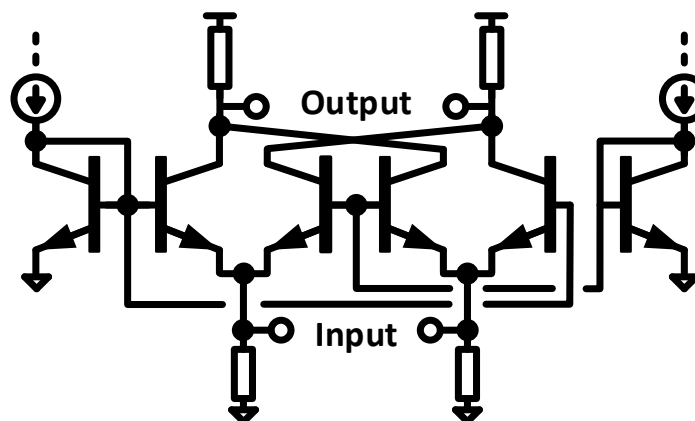
Low-power T/R switching



VGA / switch

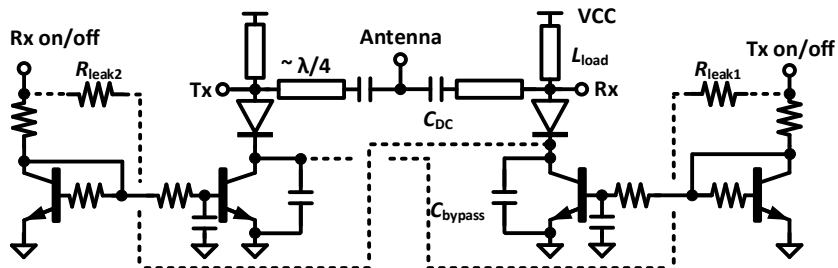


Multiplier \rightarrow mixer, modulator, phase-shifter

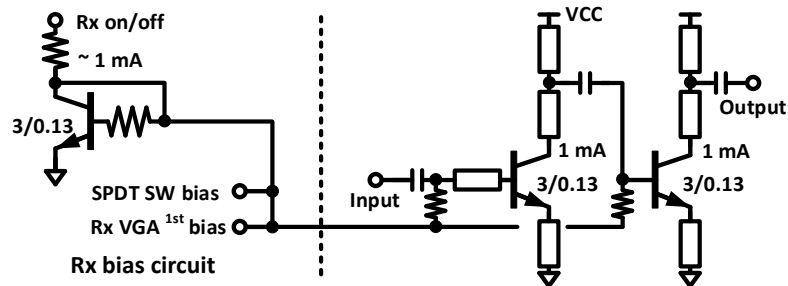


Low-power, low-voltage mm-wave design

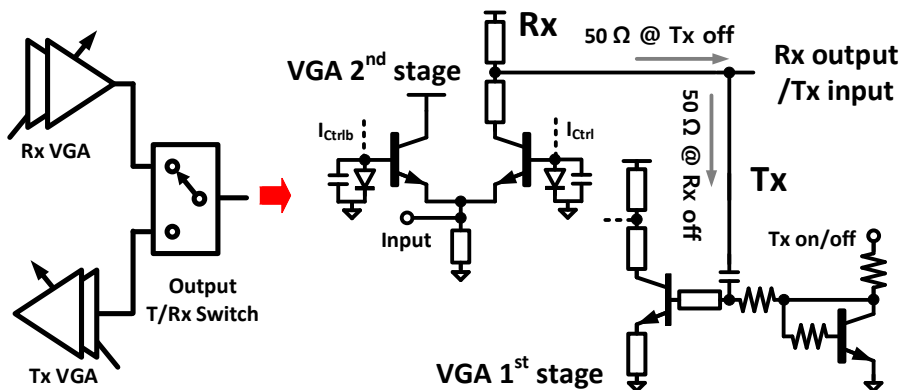
Antenna switch



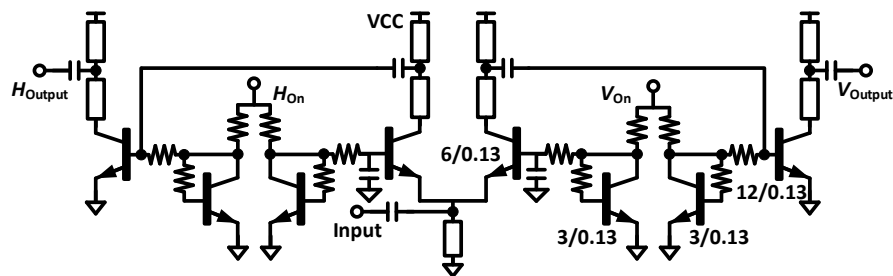
LNA



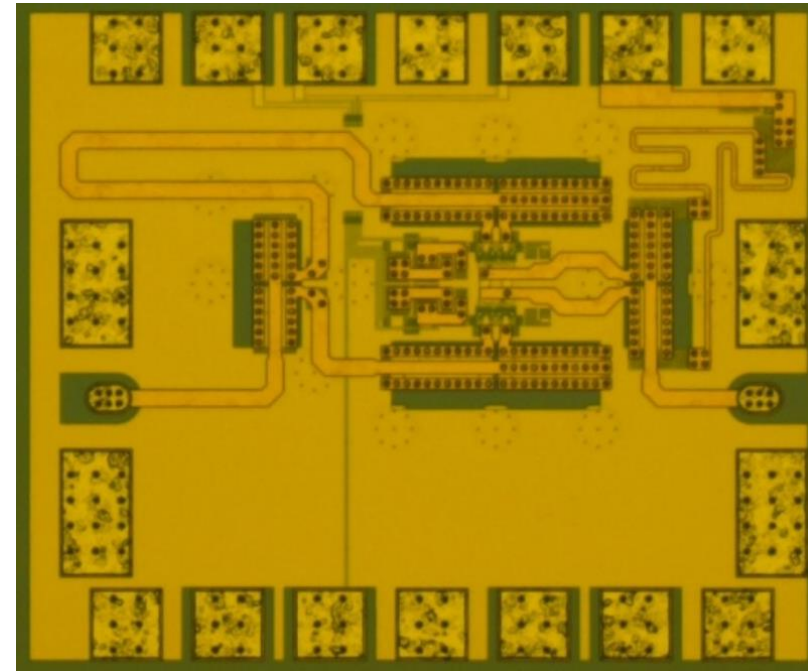
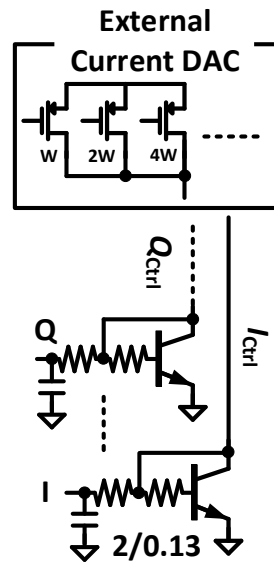
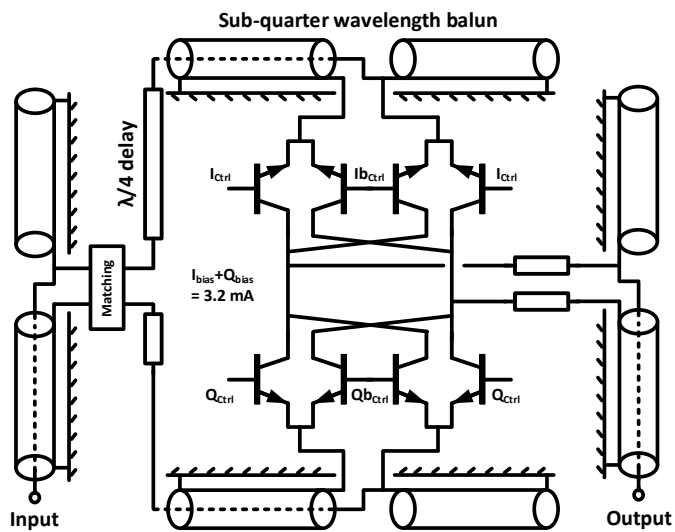
backplane T/R switch



PA & V/H switch

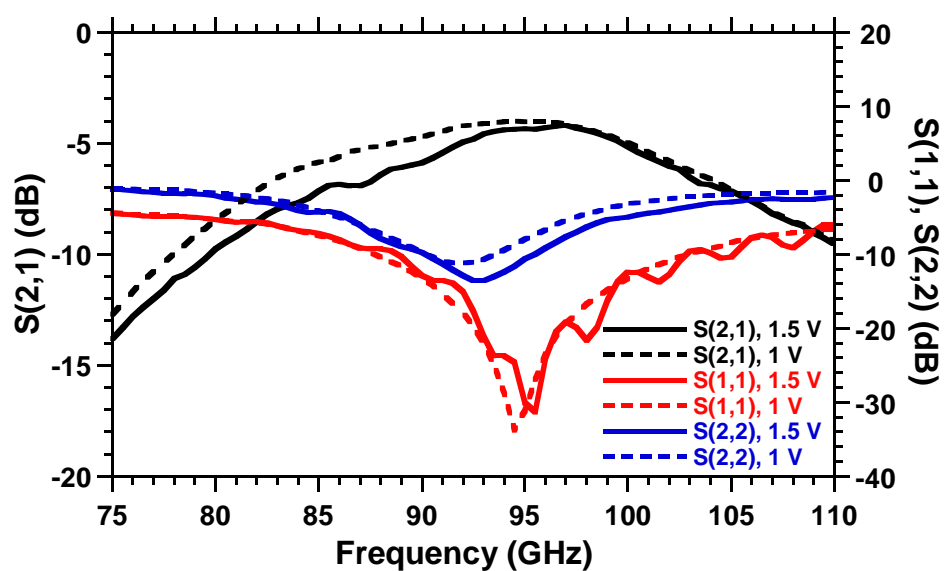
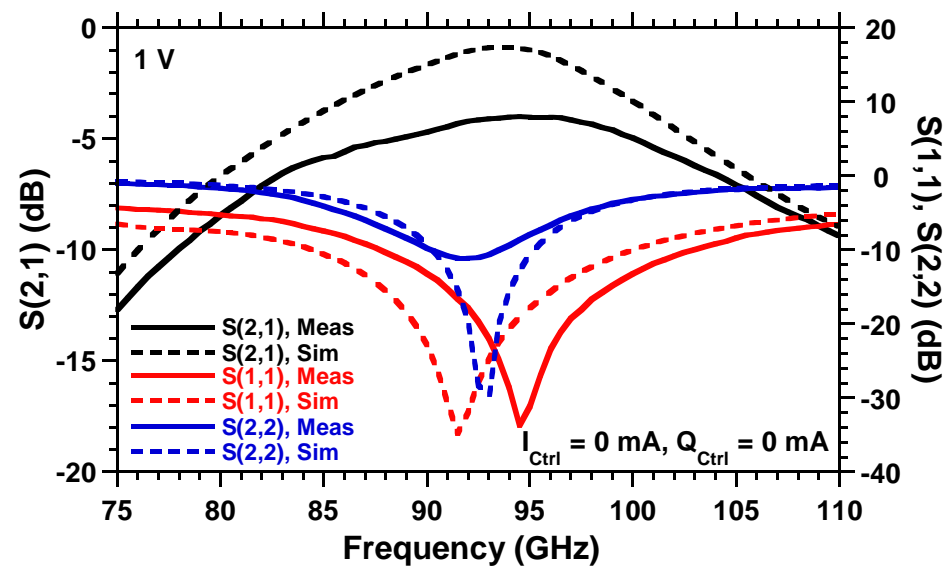
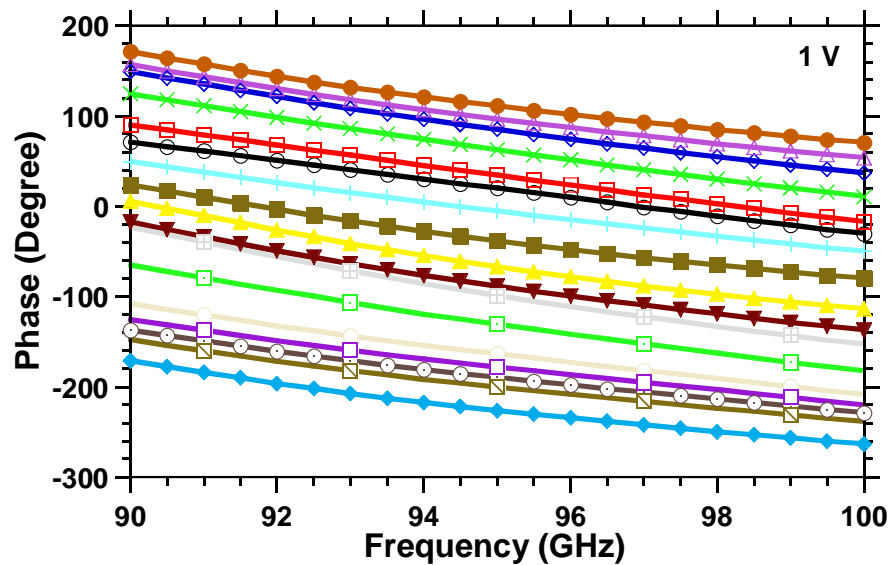
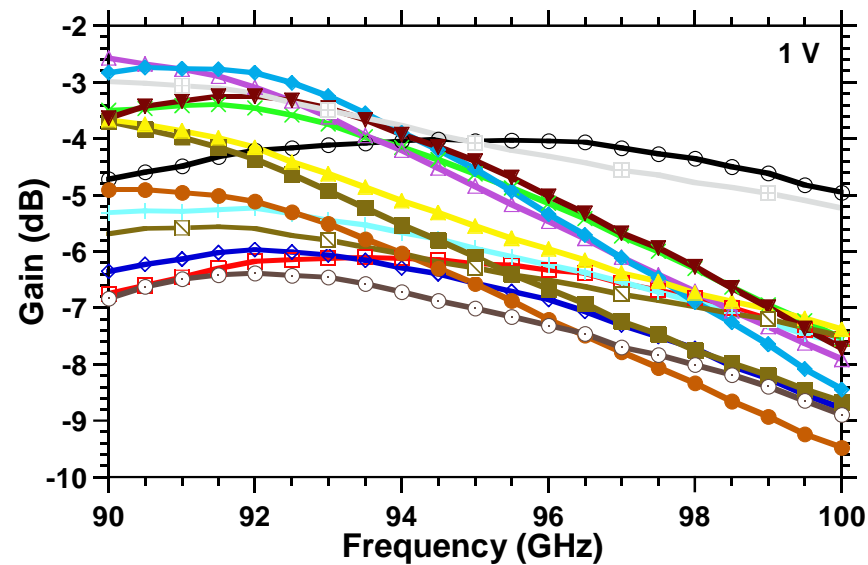


Phase-shifter and control circuits



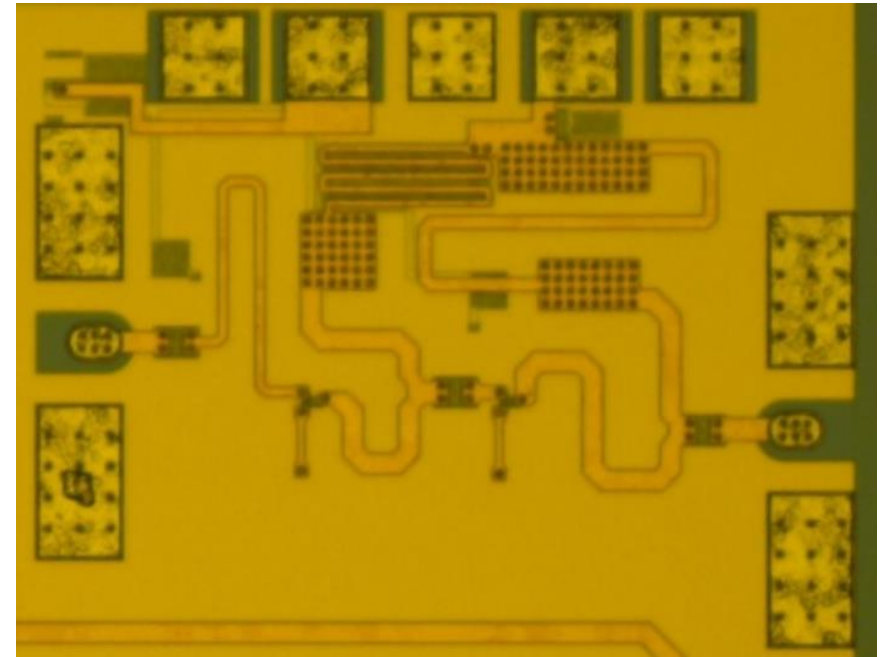
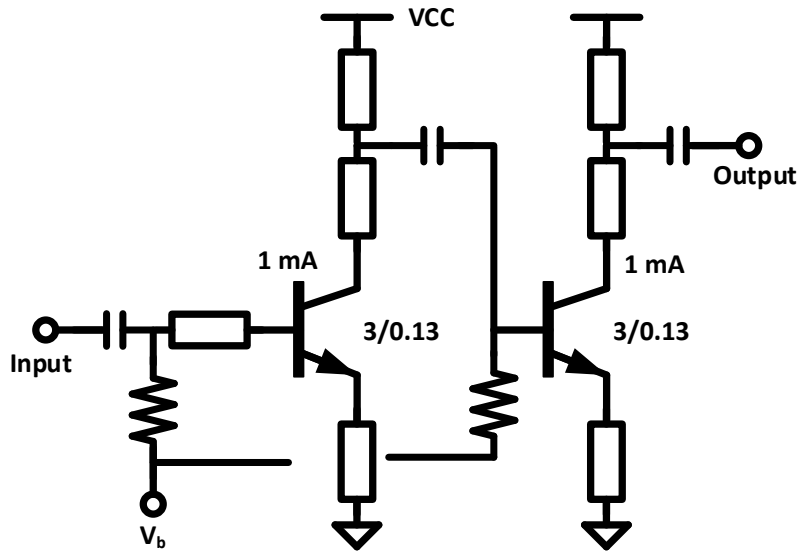
760 um x 640 um

Phase-shifter measurement results (1 V)



Power consumption: 4.2 mA @ 1 V

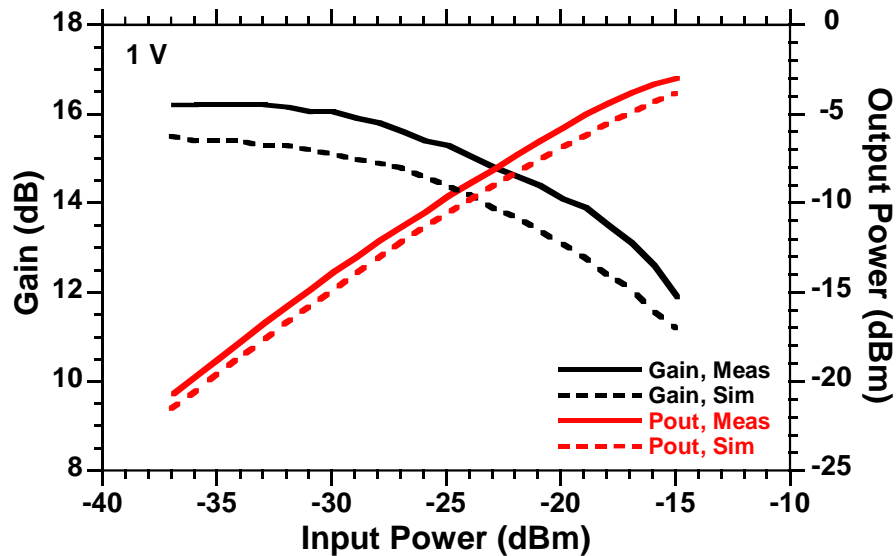
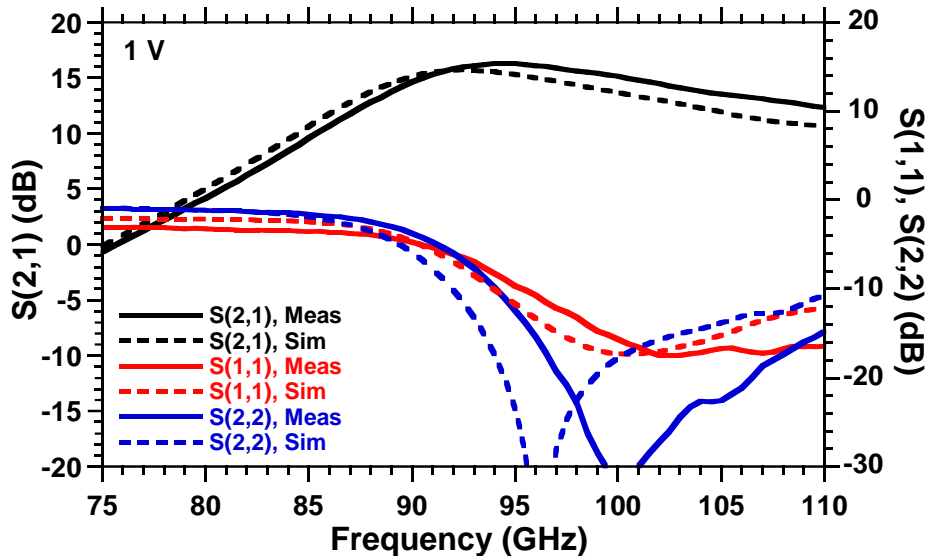
Low-noise amplifier



660 um x 510 um

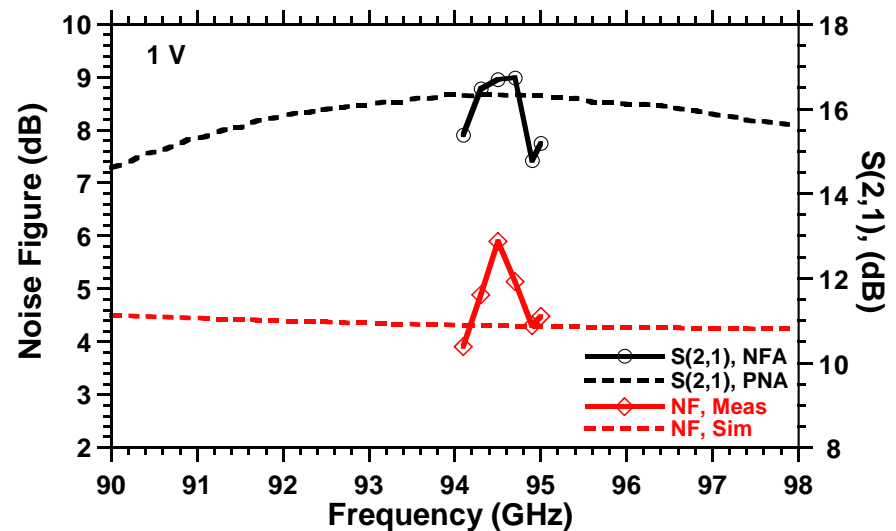
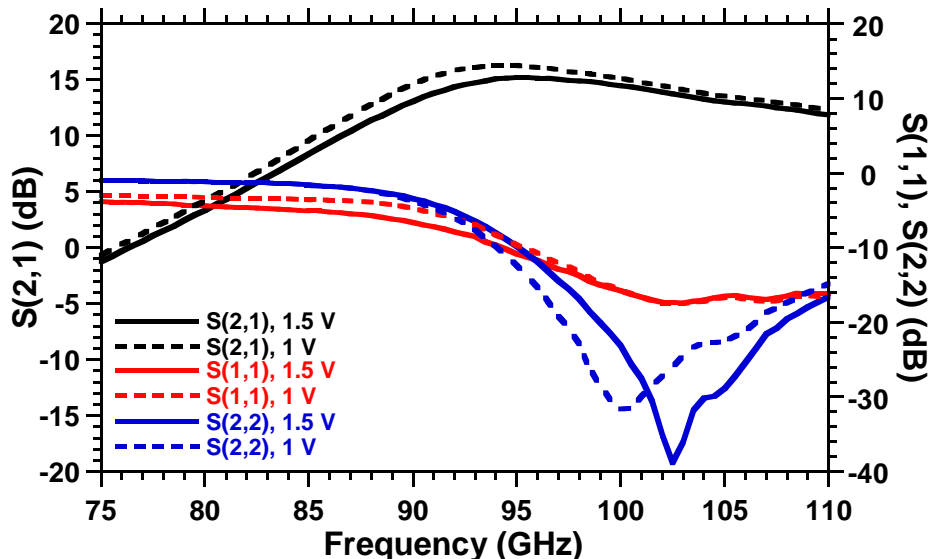
- Noise matching for input
- Conjugate matching for inter-stage
- Gain matching for output
- Power consumption: 2 mA @ 1.5 V

LNA Measurement results (1 V)

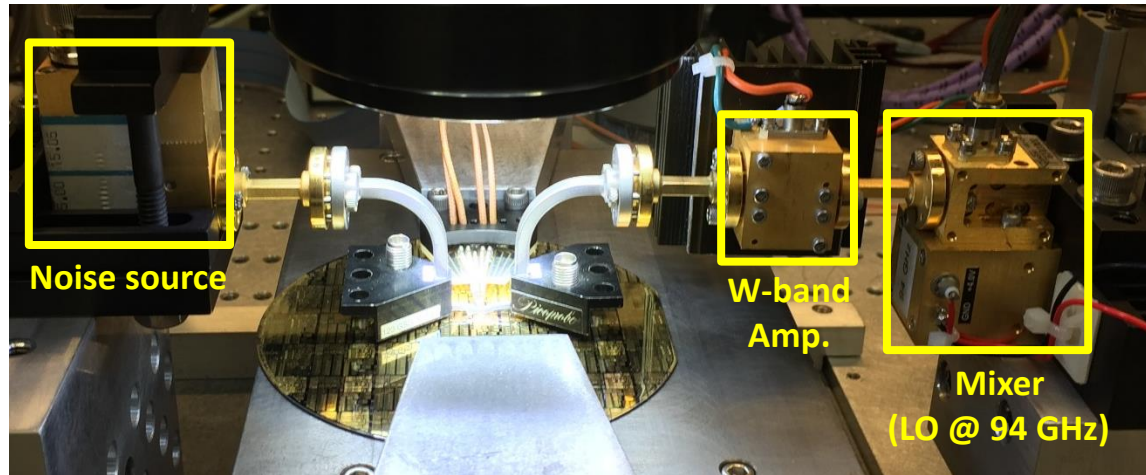


Power consumption: 2.0 mA @ 1 V

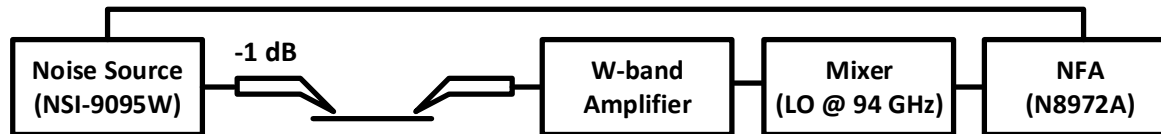
Gain: 16.3 dB @ 94 GHz (peak gain)



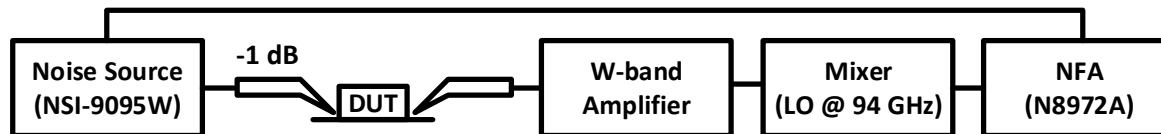
Noise measurement setup



Calibration

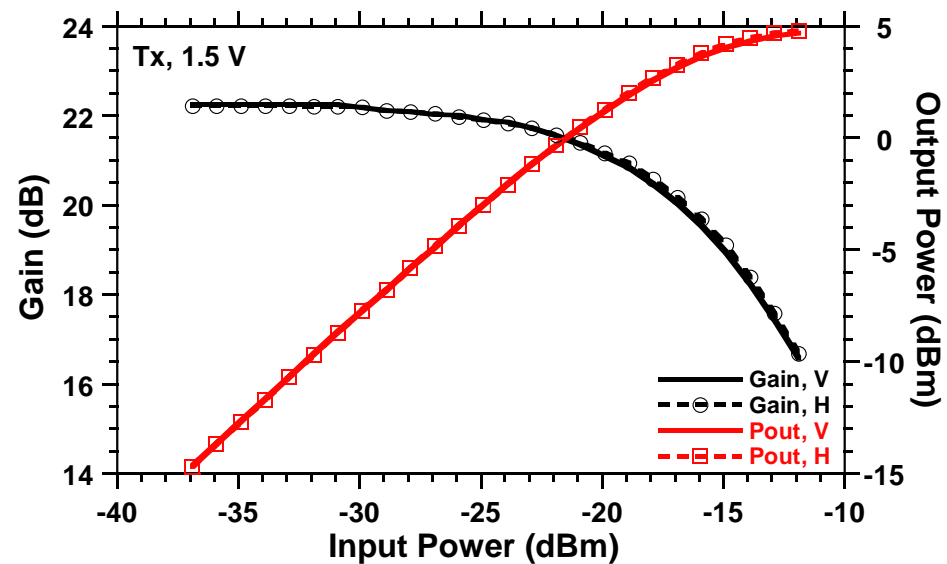
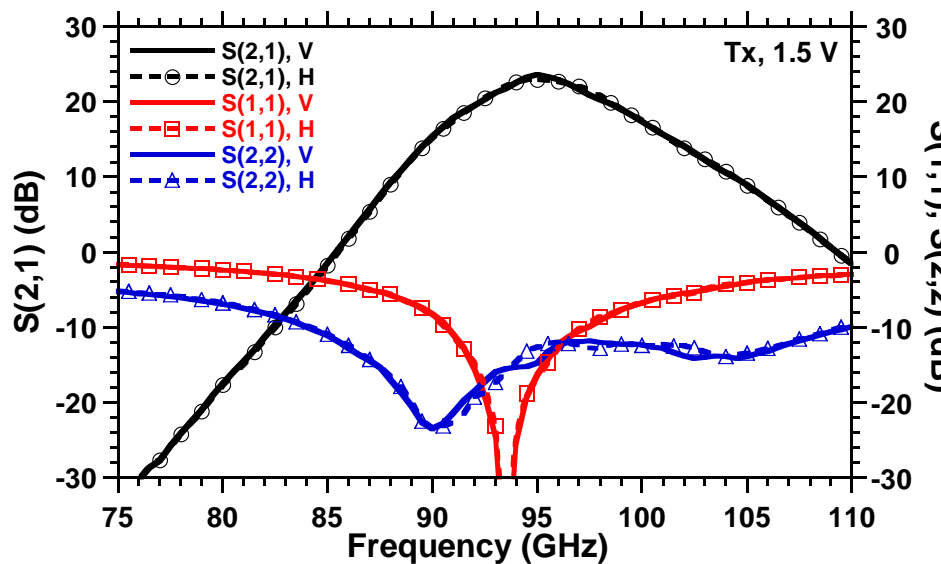
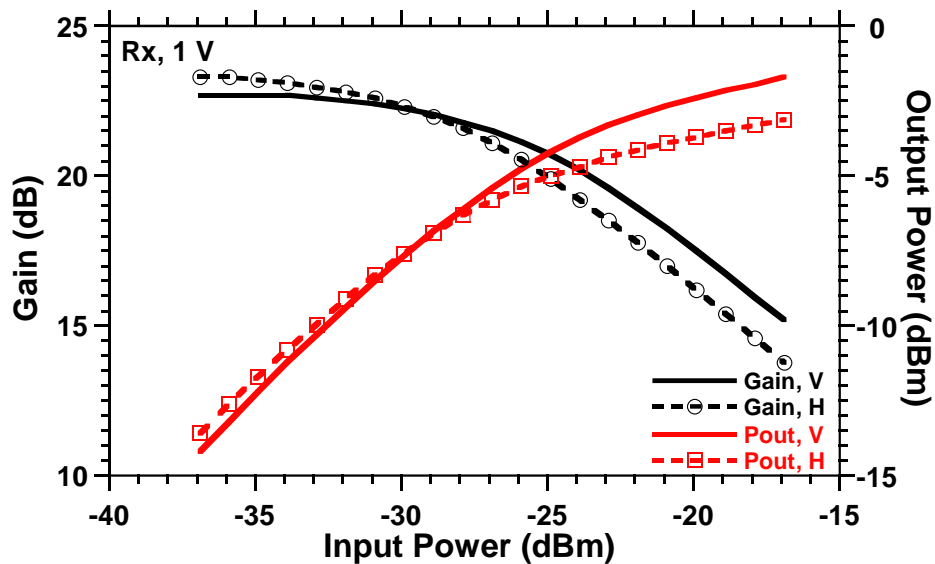
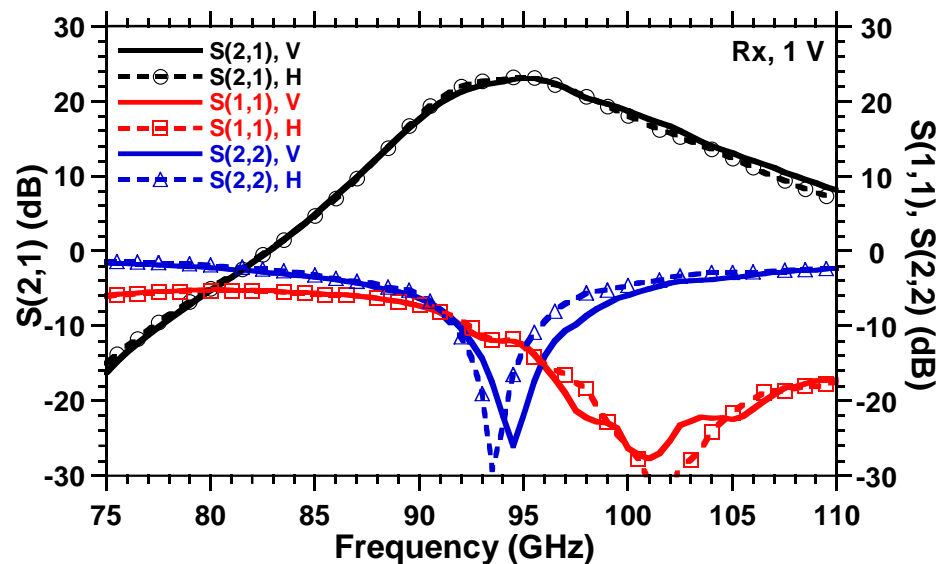


Measurement

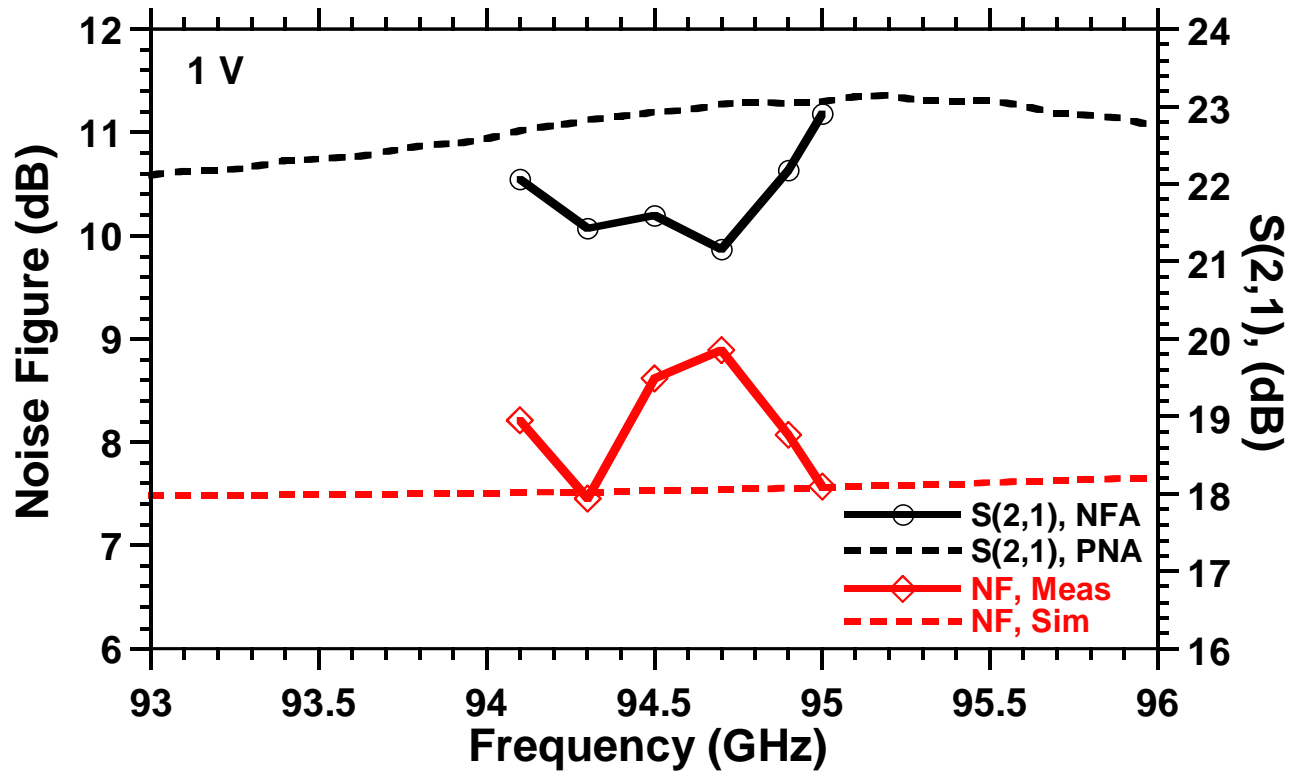


Loss before the DUT: compensated using the NFA's internal function therefore, measured gain should be subtracted by -1 dB

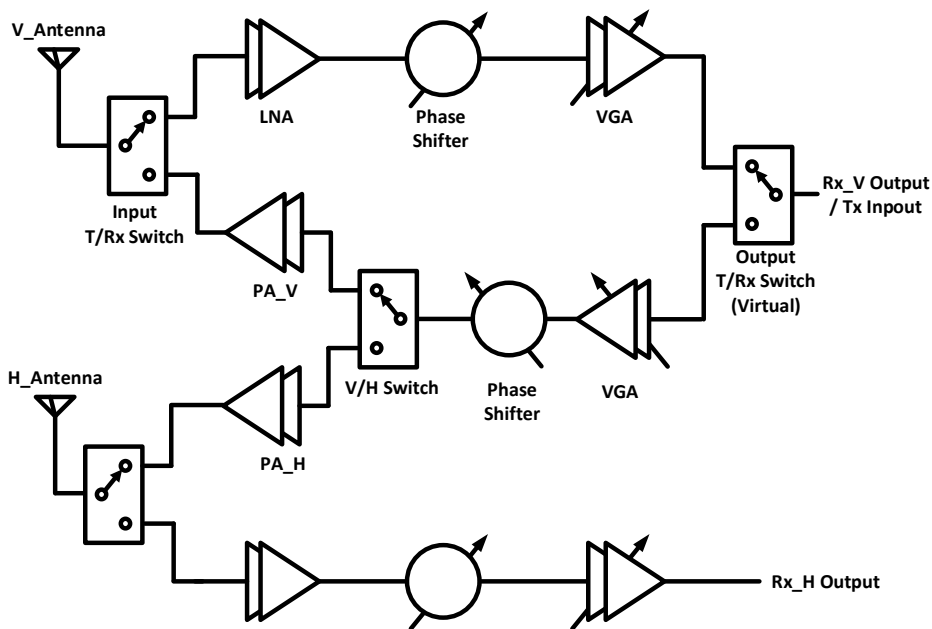
Transceiver measurement results



Receiver noise



94 GHz transceiver: performance summary

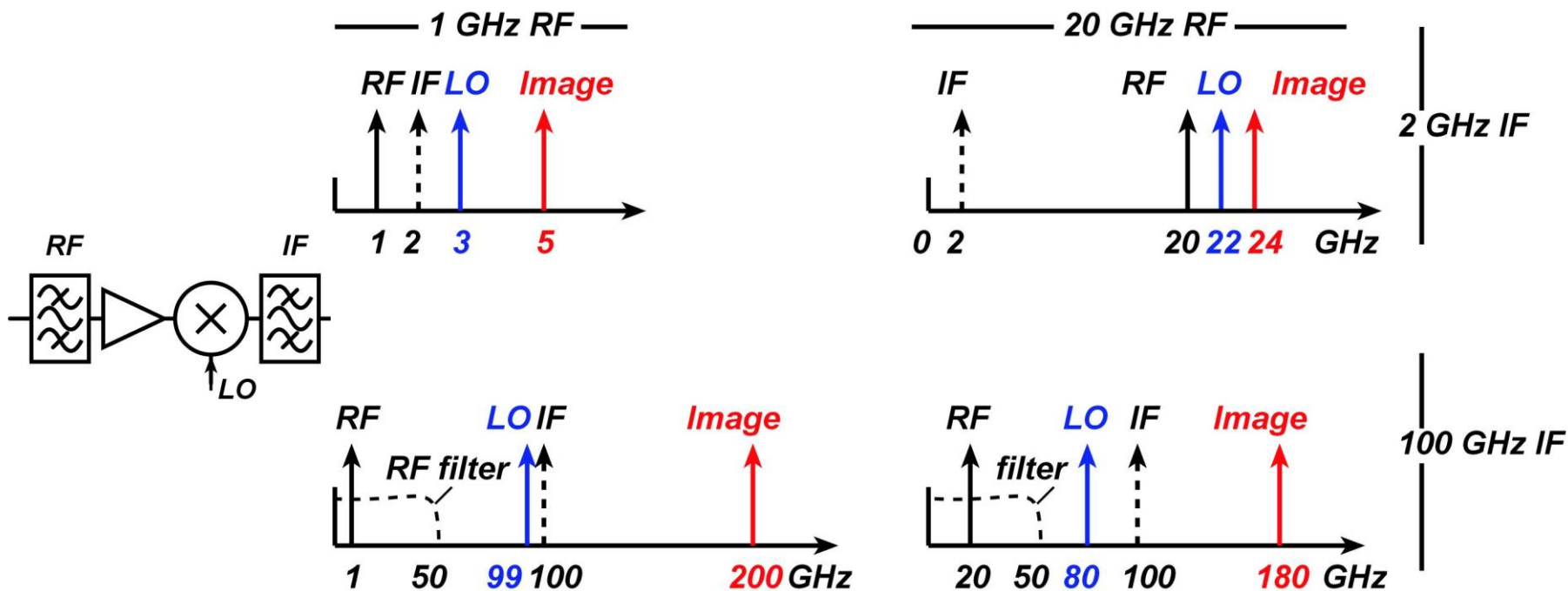


			@Vcc=1.5V	@Vcc=1.0V
Power Amplifier + v/H SW	Output Power P3dB	dBm	6.9	3.5
	Power Gain @P3dB	dB	14	14
	PAE	%	17	12.7
	Pdiss @ P3dB	mW	27.2	16.9
	Pdiss (small-signal)	mW	22.5	16.4
	Pdiss (core exclude bias ckt)	mW	17.55	11.45
	Size (exclude Pads)	µm	475*475	475*475
VGA	Power Gain (Rx/Tx)	dB	12.5/10.9	13.4/11.5
	NF (max gain)	dB	4.8/7.8	4.6/7.7
	NF (max gain - 6dB)	dB	7.1/9.4	6.6/9.3
	Input P1dB	dBm	-12.4/-9.6	-15.9/-15
	OIP3	dBm	6.7/7.6	-1.8/-3
	Pdiss	mW	9	6.4
	Pdiss (core exclude bias ckt)	mW	6.9	4.6
Size (exclude Pads)	µm	530*900	530*900	
LNA	Power Gain	dB	15.1	16.3
	NF	dBm	5	5
	Input P1dB	dBm	-21.9	-24.5
	OIP3	dBm	-1.7	-3
	Pdiss	mW	4.95	3.95
	Pdiss (core exclude bias ckt)	mW	3.5	2
Size (exclude Pads)	µm	480*280	480*280	
Phase Shifter	Power Gain (Rx/Tx)	dB	-5±1.5	-5±1.5
	NF	dB	14.9	14.6
	Input P1dB	dBm	9	6
	OIP3	dB	10.9	2
	Pdiss	mW	6.5	4.2
	Pdiss (core exclude bias ckt)	mW	6.5	4.2
Size (exclude Pads)	µm	660*340	660*340	
SPDT Antenna T/Rx SW	Loss	dB	2	1.8
	Isolation	dB	19.5	18.5
	P1dB	dBm	14	14
	Pdiss	mW	6.8	4.8
	Pdiss (core exclude bias ckt)	mW	4.8	2.8
Size (exclude Pads)	µm	200*680	200*680	
Rx Channel	Power Gain	dB	21	22.7
	NF	dB	8.5	8
	Fractional BW	%	7.6	7.5
	Input P1dB	dBm	-22.9	-27.9
	IIP3	dBm	-16.3	-24.3
	Pdiss	mW	19.2	12.9
Pdiss (core exclude bias ckt)	mW	17.25	11	
Tx Channel	Power Gain	dB	22.2	22.4
	Pout (P3dB)	dBm	3.8	0.1
	Fractional BW	%	6.7	6.7
	Output P1dB	dBm	0.8	-3.4
	OIP3	dBm	10	3.8
	Pdiss	mW	39.7	28.7
	Pdiss (core exclude bias ckt)	mW	31.5	20.5

Simulation

**IC example:
1-25 GHz
dual-conversion
receiver**

Dual Conversion: Wide Tuning



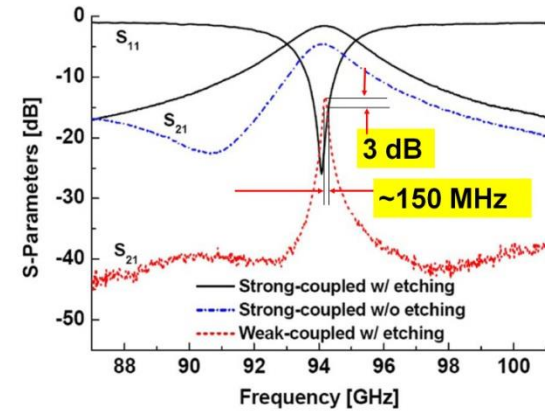
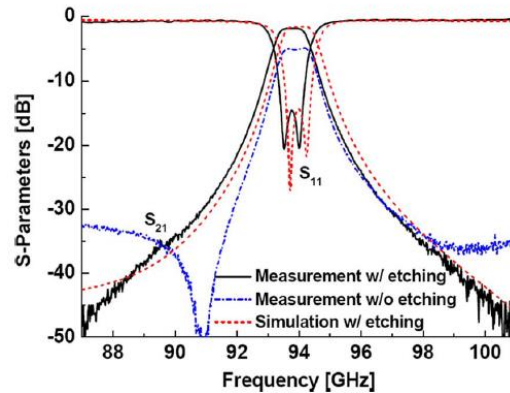
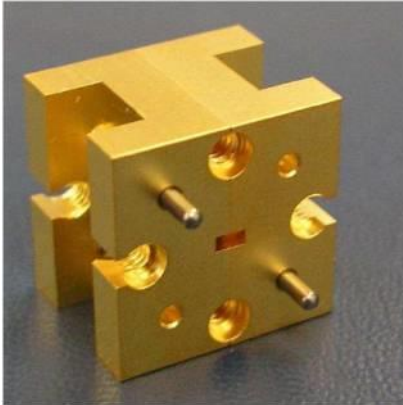
Low (2GHz) IF → image & LO responses close to RF carrier

High (100GHz) IF → image & LO responses far from RF carrier

Dual conversion: a standard approach in RF receivers.

Modern THz IC processes → 100 GHz IF easily feasible
→ Image-response-free 1-50 GHz receiver

W-band Waveguide Filters



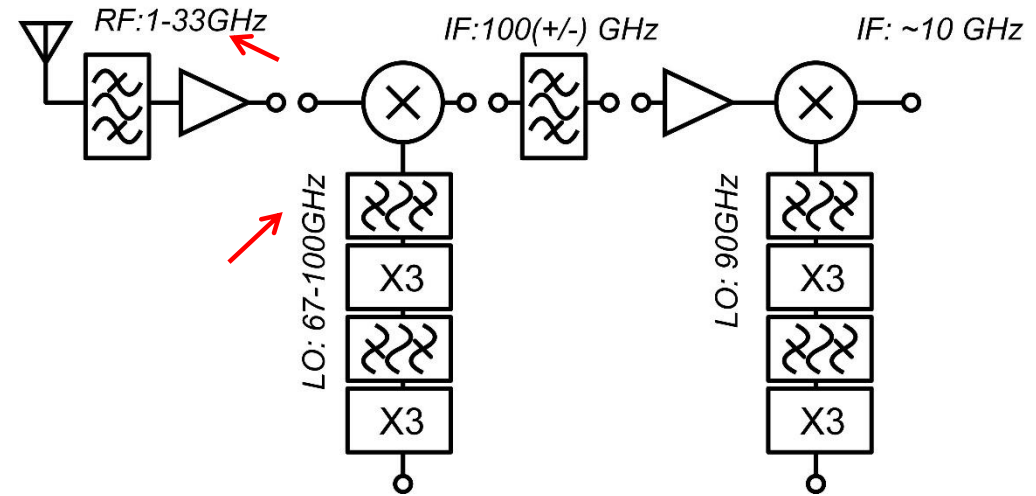
1 GHz filter bandwidth is easy; 100 MHz should be just feasible.

our effort: design the ICs, purchase the filter.

Choice of Frequency Plan

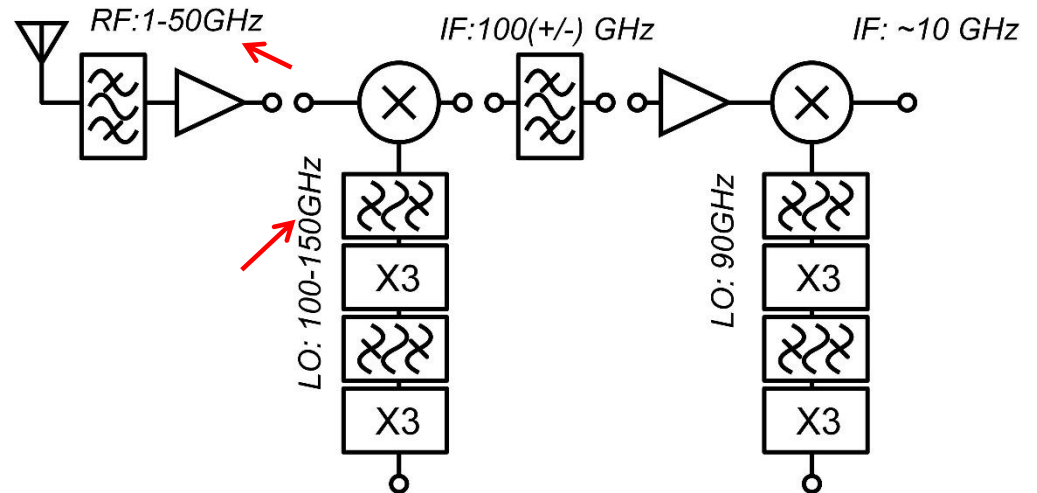
LO below IF:

tripplers have residual output @ $2f_{in}$
→ maximum 1.5:1 tuning ratio
→ maximum 67-100 GHz LO tuning
~1-33 GHz RF tuning
Need 67-100GHz LO driver PA
present designs (lower-risk)

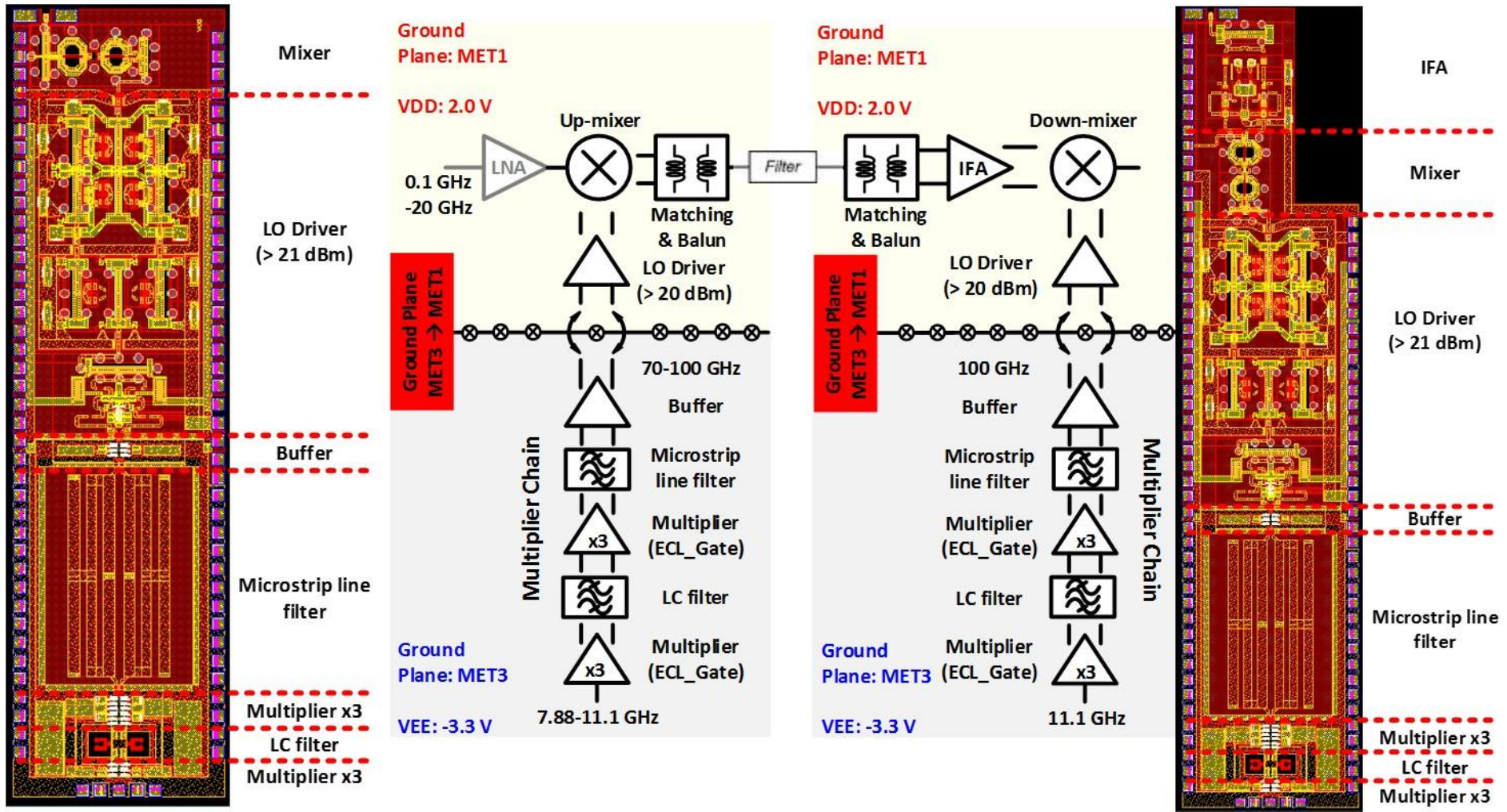


LO above IF:

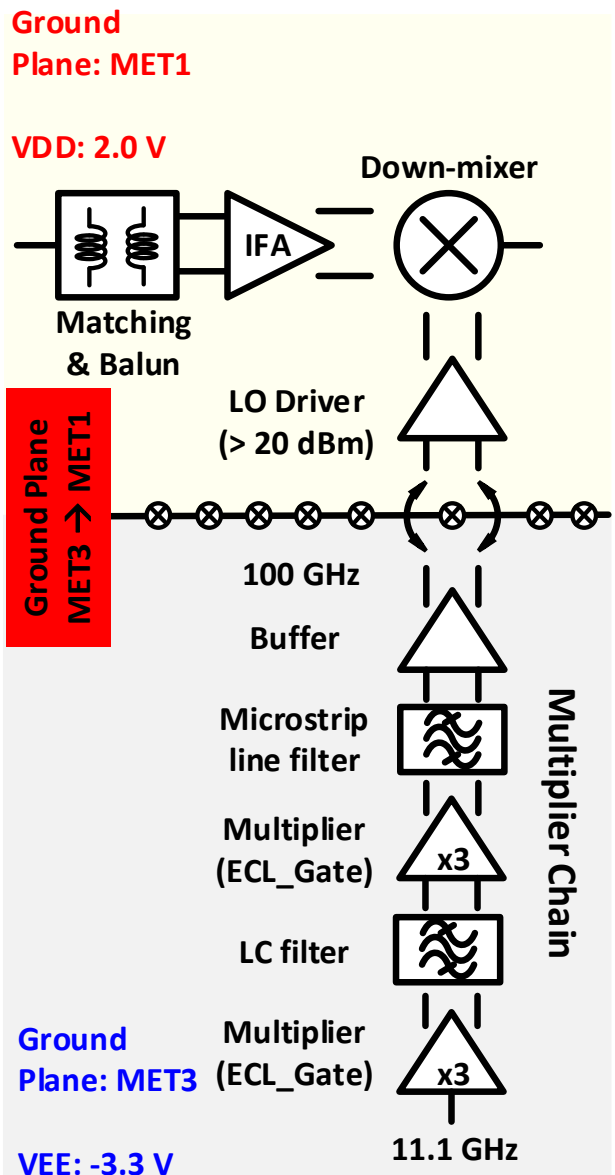
maximum 100-150 GHz LO tuning
~1-50 GHz RF tuning
Need 100-150GHz LO driver PA
At ~200-300mW output power
higher-risk.



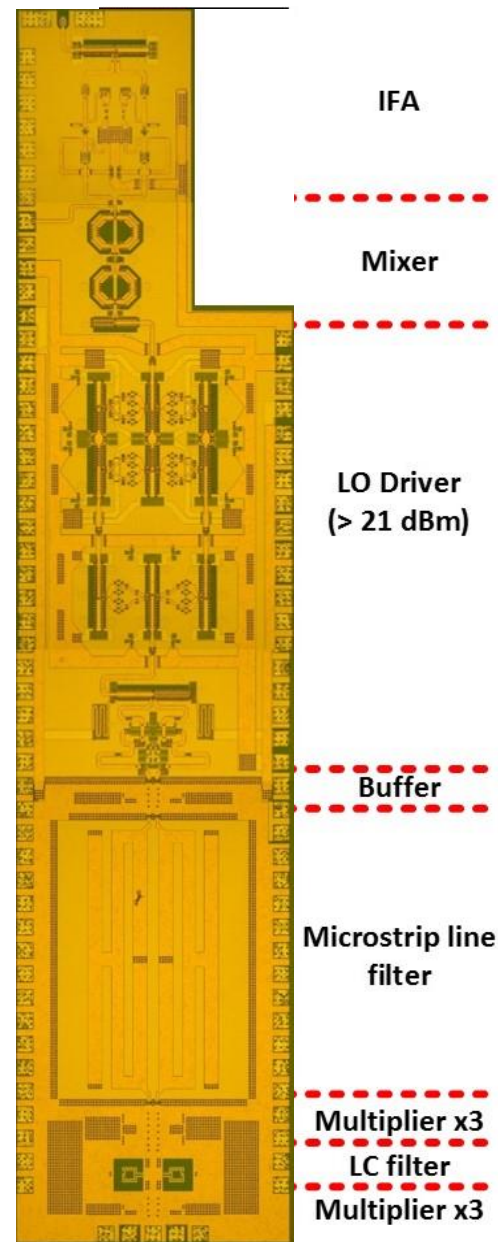
Full receiver configuration: 2 chips to ease testing



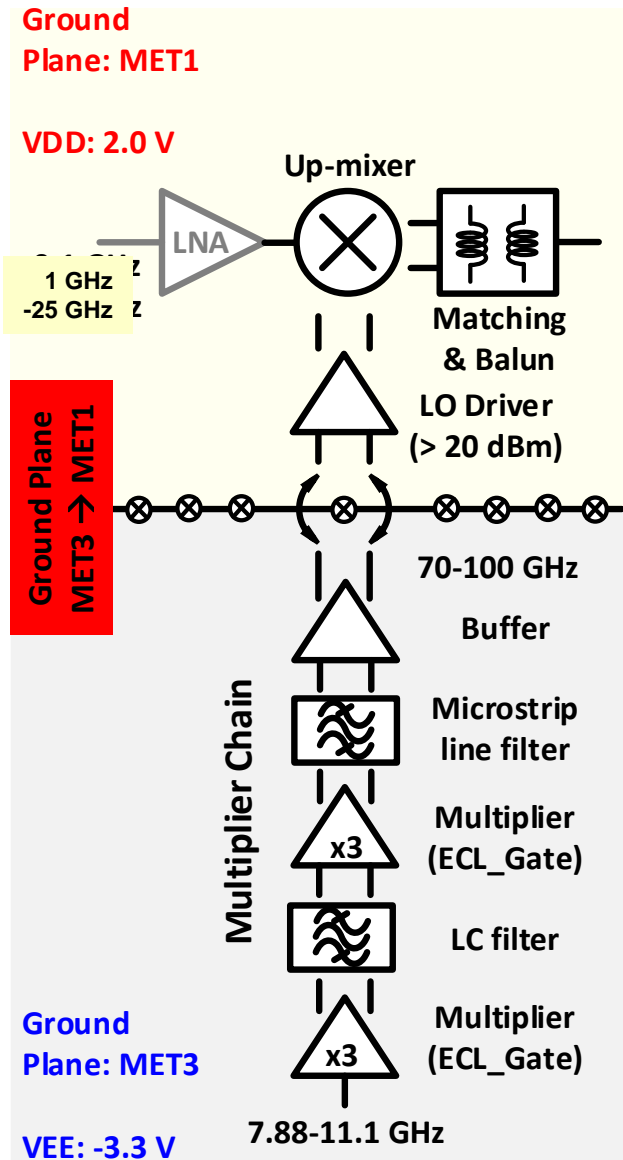
Receiver: down-conversion block



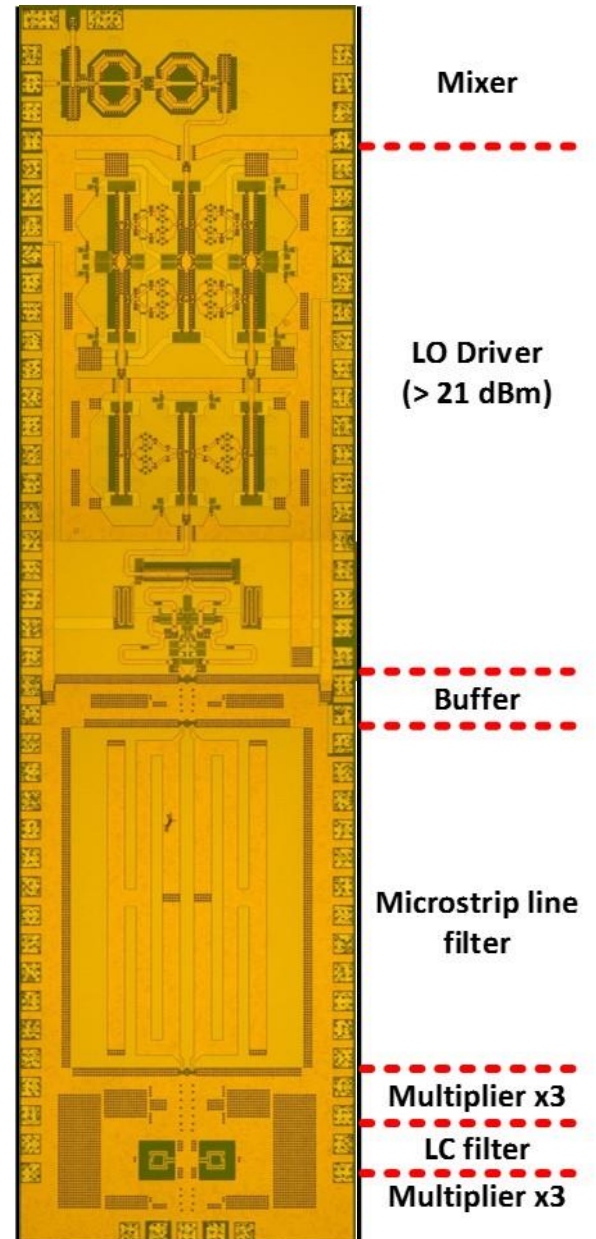
5240 um x 1160 um



Receiver: up-conversion block



4300 um x 1160 um



Mixer

Diode mixer:

High dynamic range.

base-collector diodes: no saturation

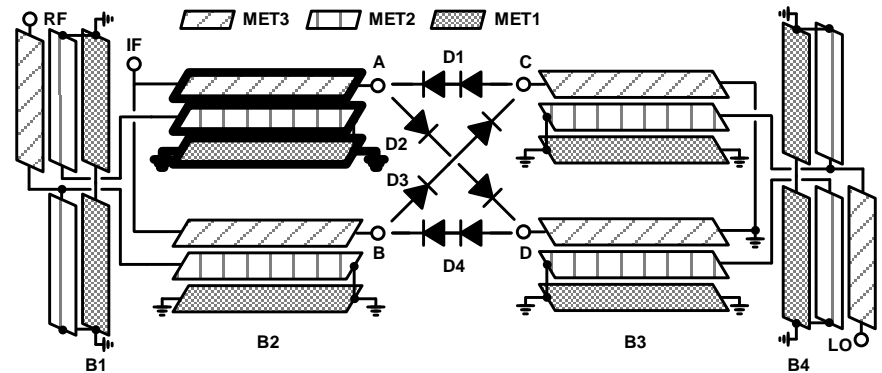
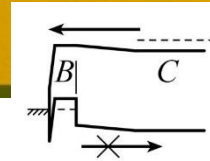
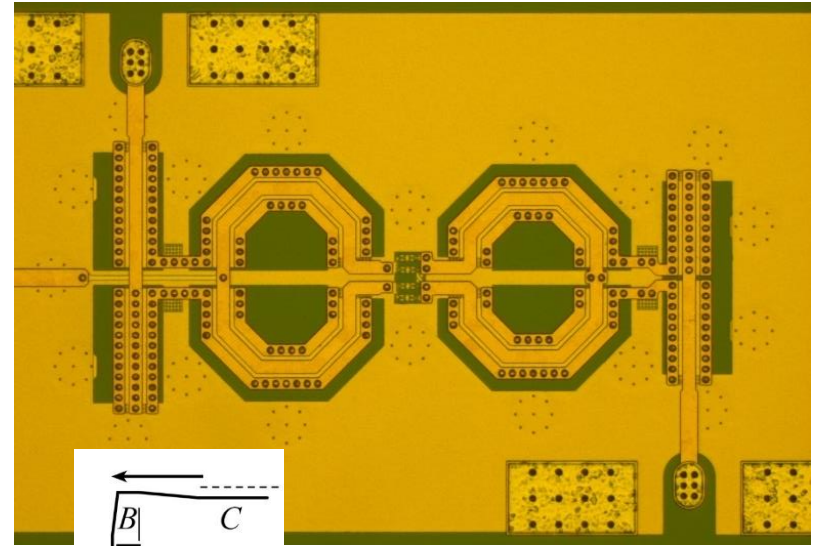
series-connected → high IP3

requires high LO drive power

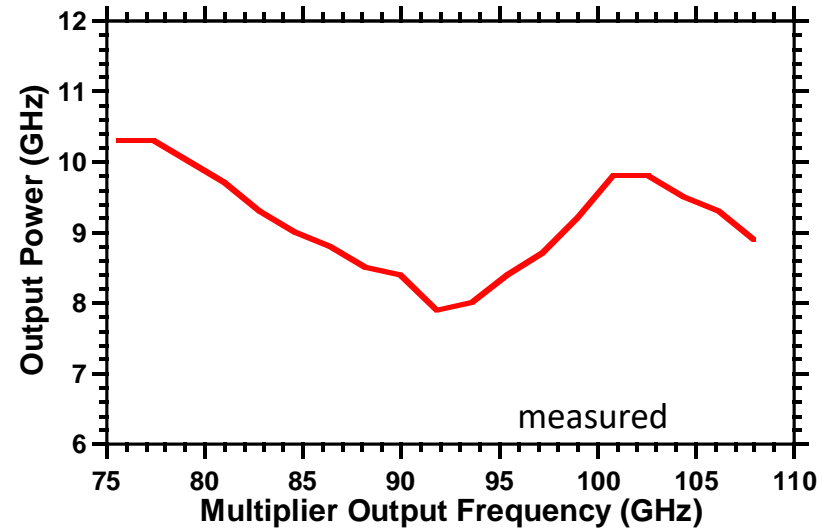
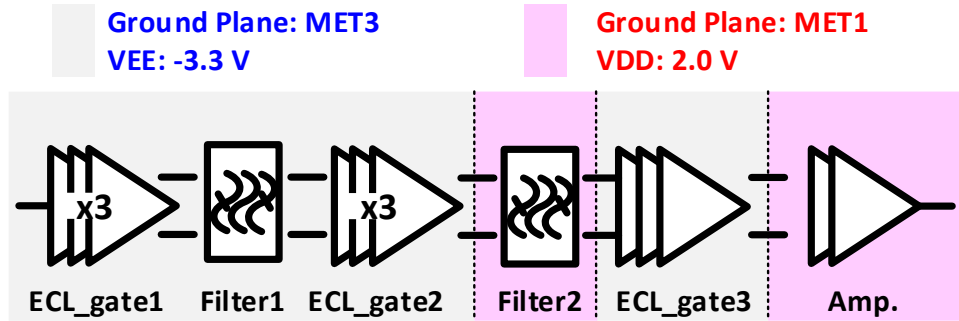
Baluns:

tri-plane design

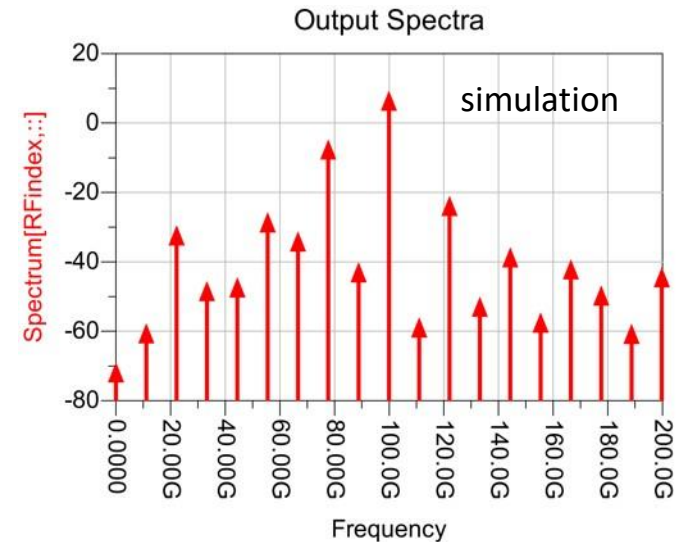
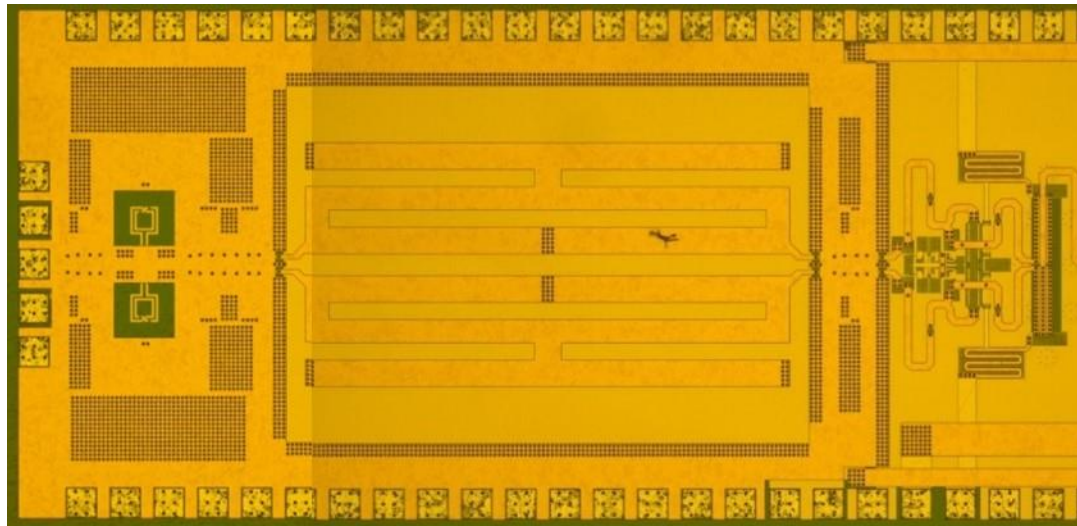
some are sub-quarter-wavelength



9:1 LO Multiplier



2500 um x 1160 um



Differential LO Driver Amplifier: 67-100GHz

Ultra-broadband LO driver

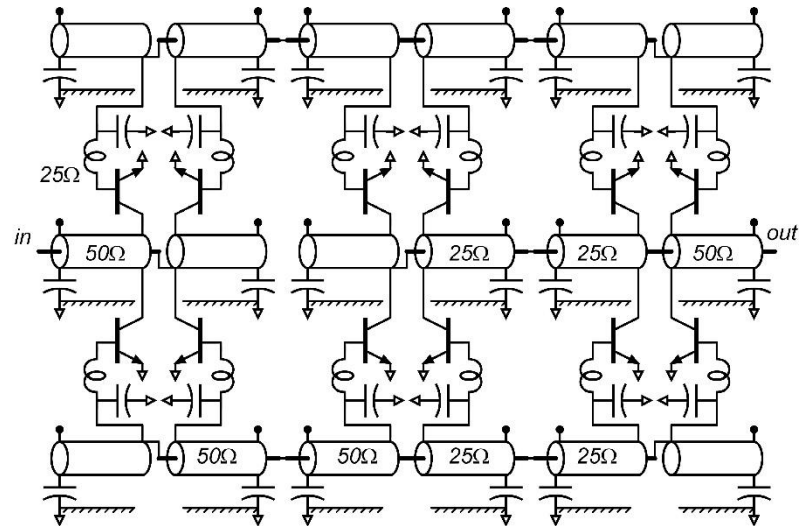
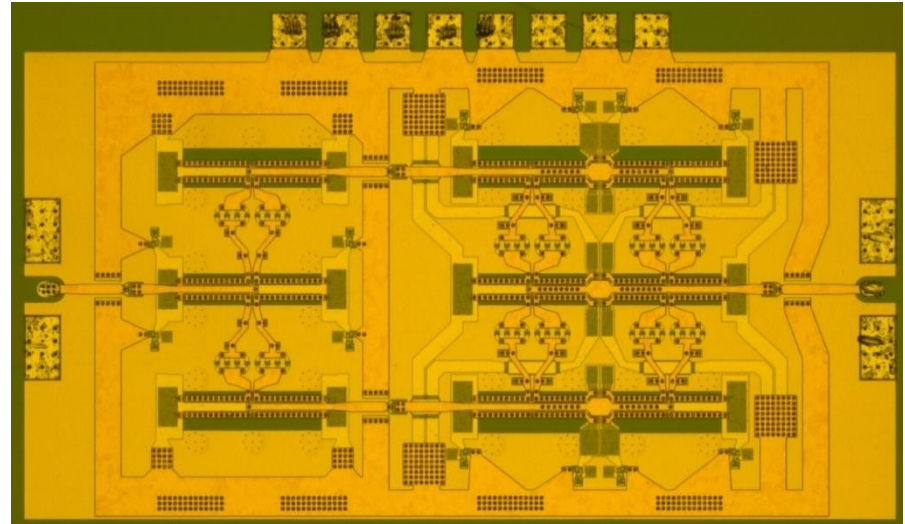
limited by 67GHz substrate mode ?
data shows otherwise.

High Power

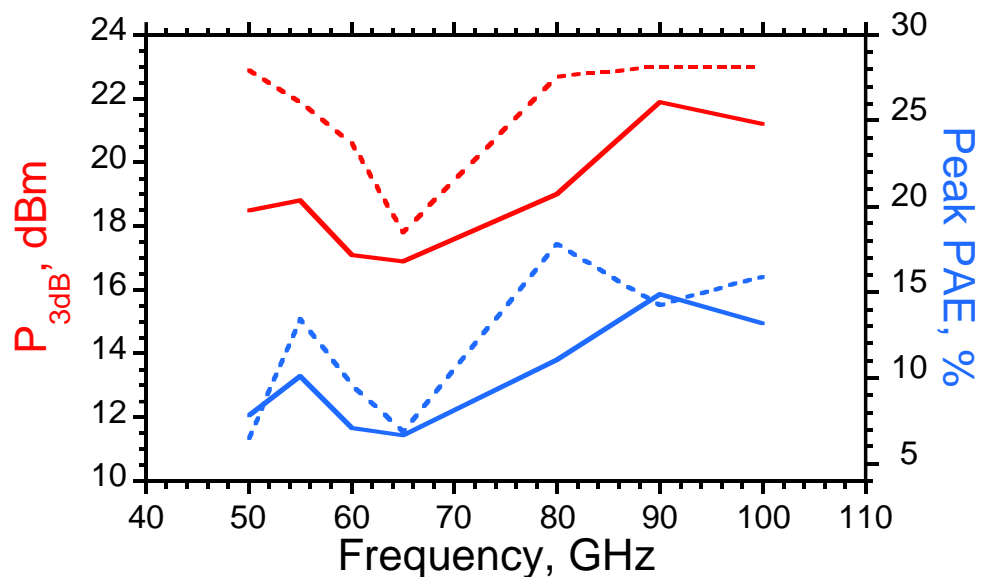
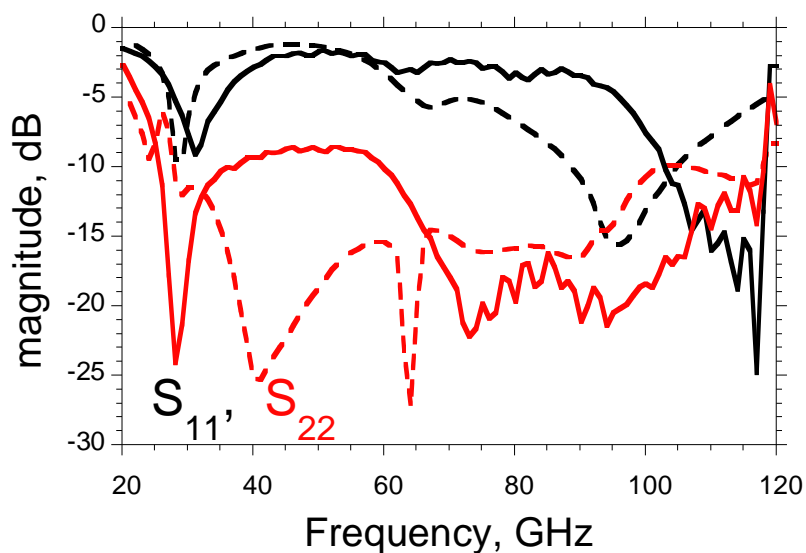
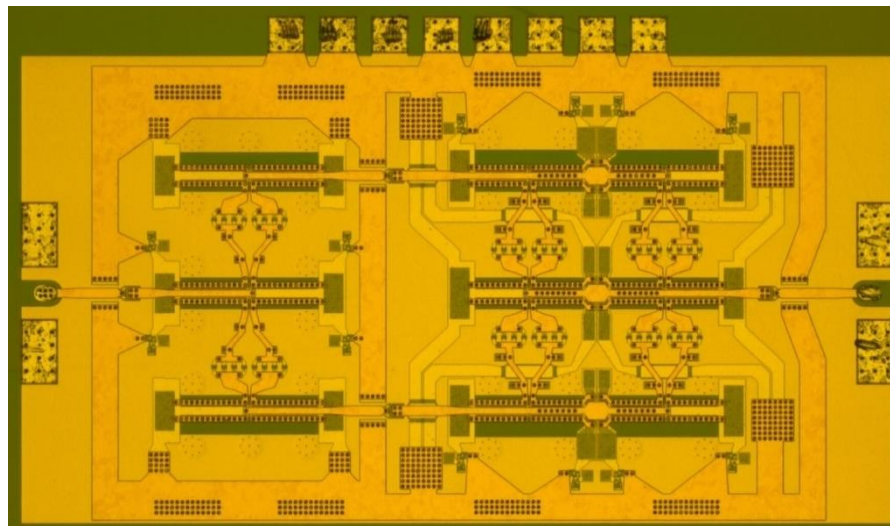
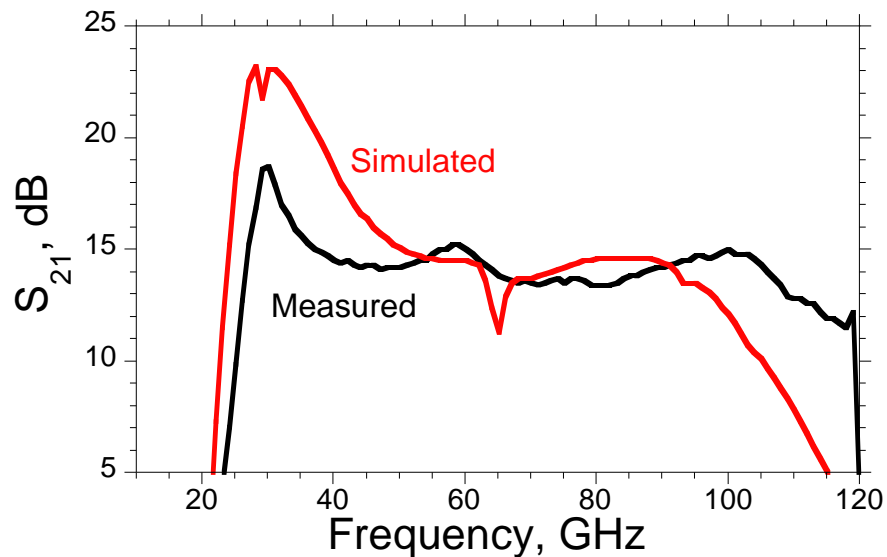
required by high-IP3 mixer
>100mW over full bandwidth
> 250mW at most frequencies.

Topology

4:1 series connected by baluns
compact, efficient, ultra-broadband
2 cascaded stages



Differential LO Driver Amplifier: 67-100GHz



High dynamic range IF amplifier

low noise figure

high third-order intercept

low/moderate gain

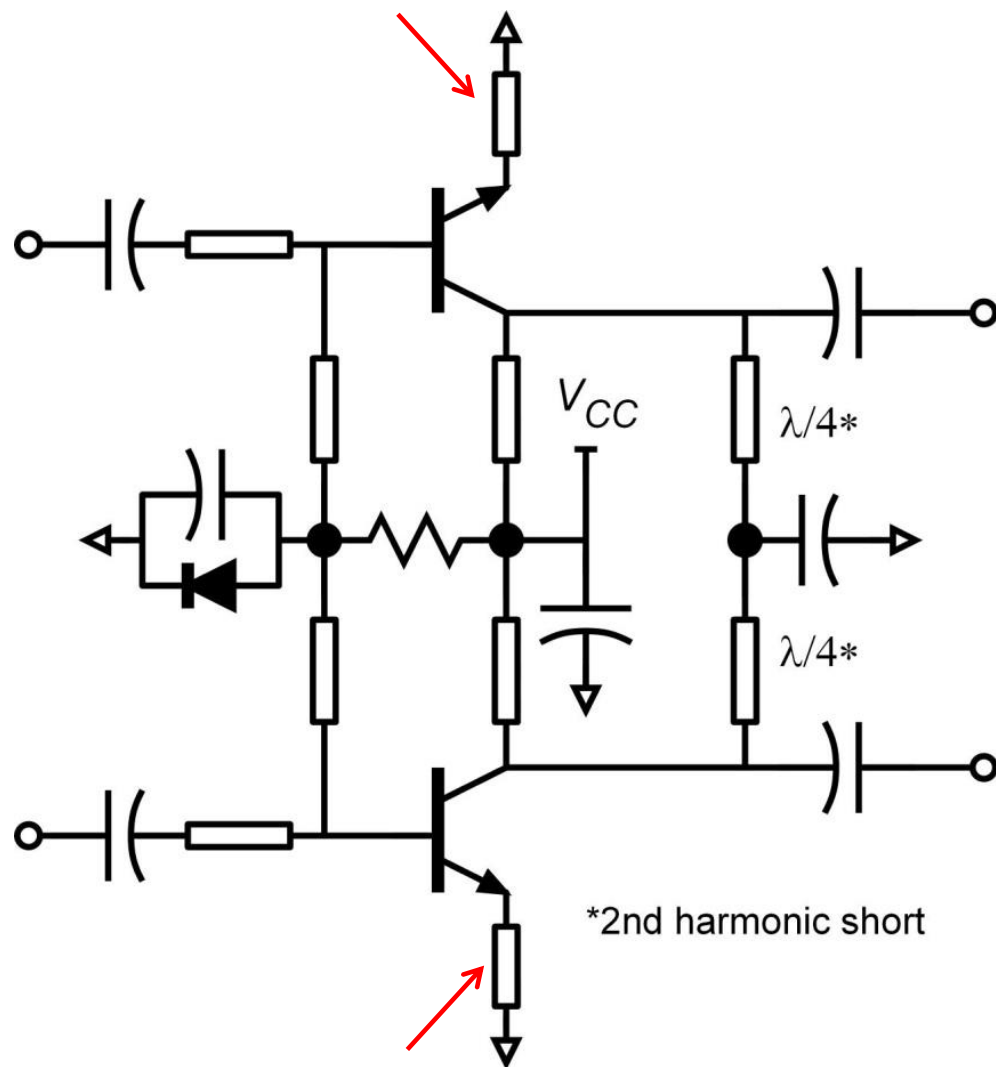
Common-emitter

Pseudo-differential

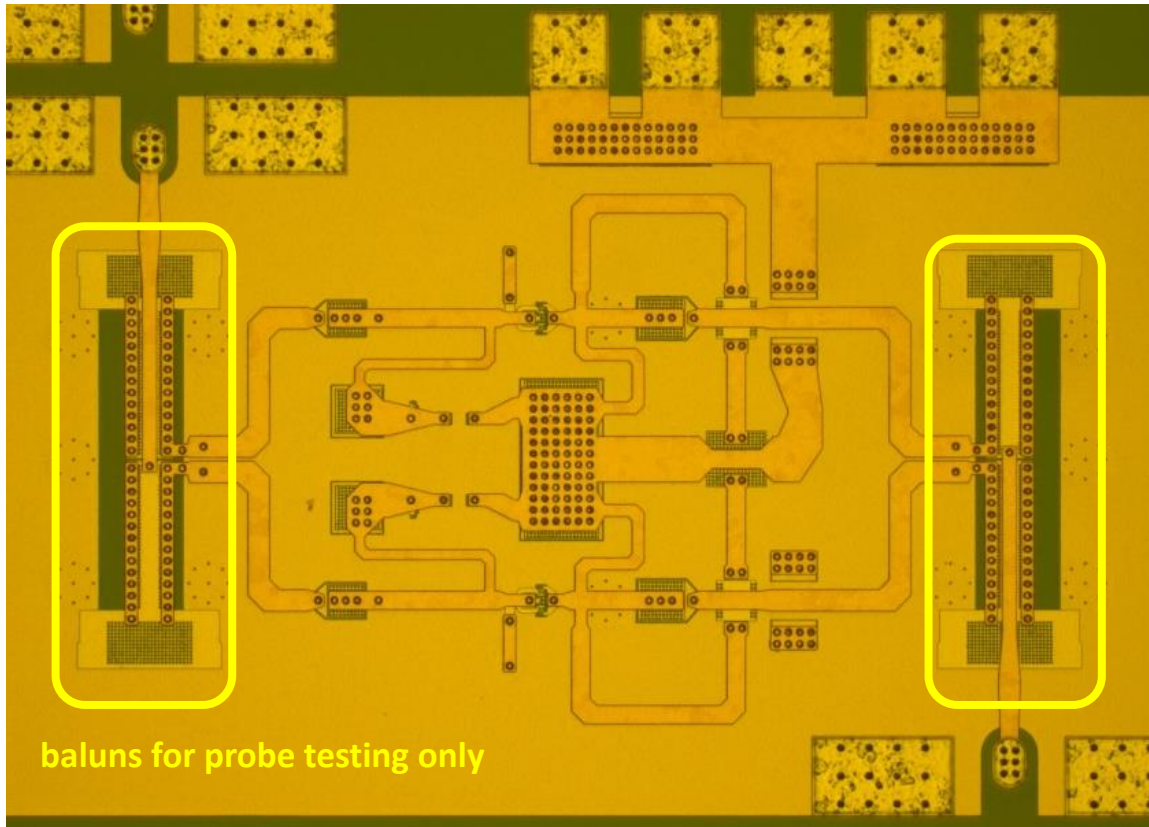
Strong **inductive degeneration**

high IP3.

partly converges noise & S_{11} tuning

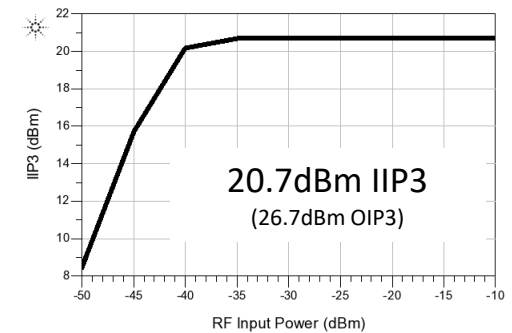
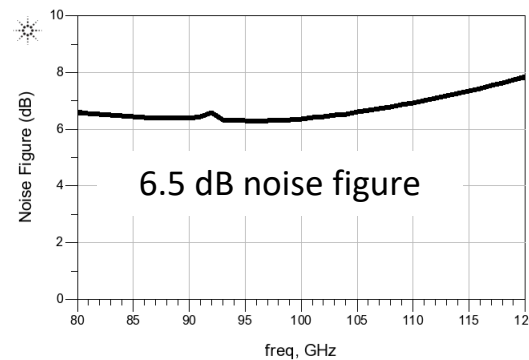
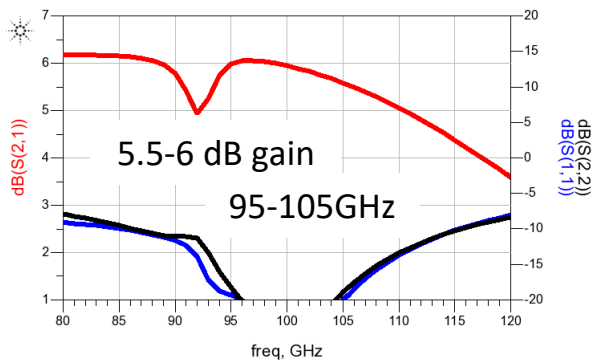


First IF Amplifier



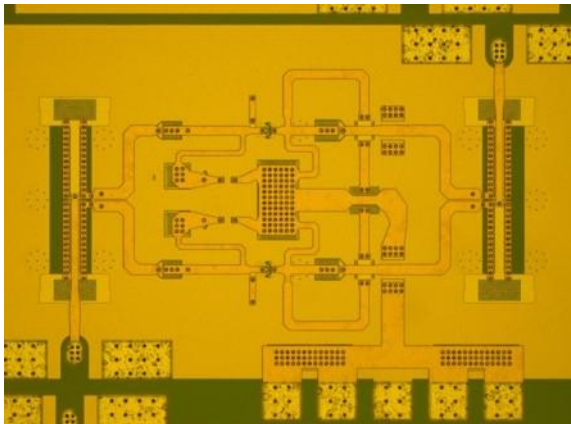
WITHOUT PADS: 551 um X 575 um,
100 mW DC power

Simulations

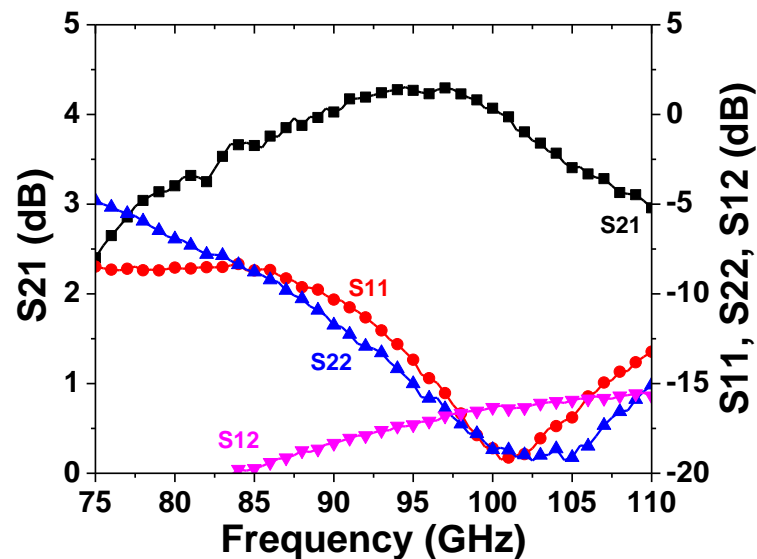


IF Amplifier measurement results

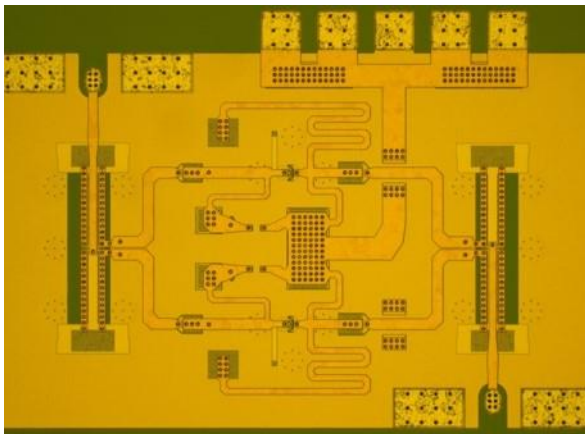
Low-gain (high-IIP3) design



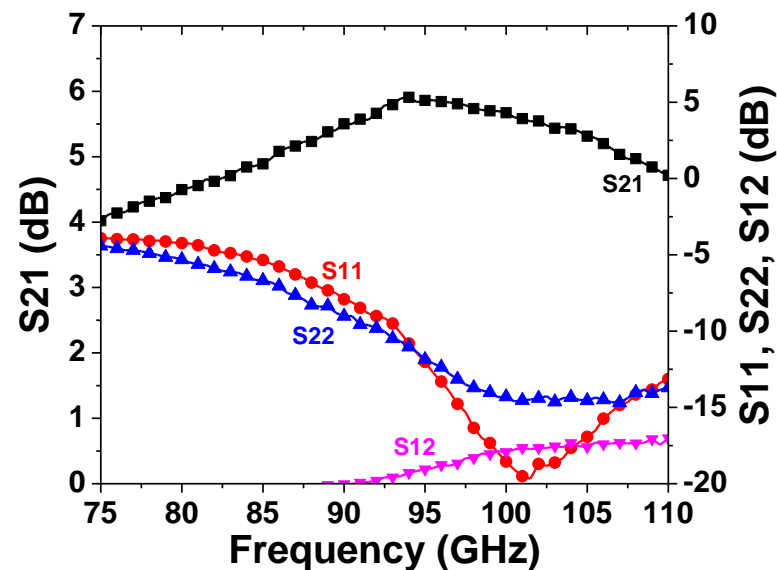
Power consumption: 94 mA @ 2 V
Peak gain: 4.3 dB @ 95 GHz, 4.0 dB @ 100 GHz



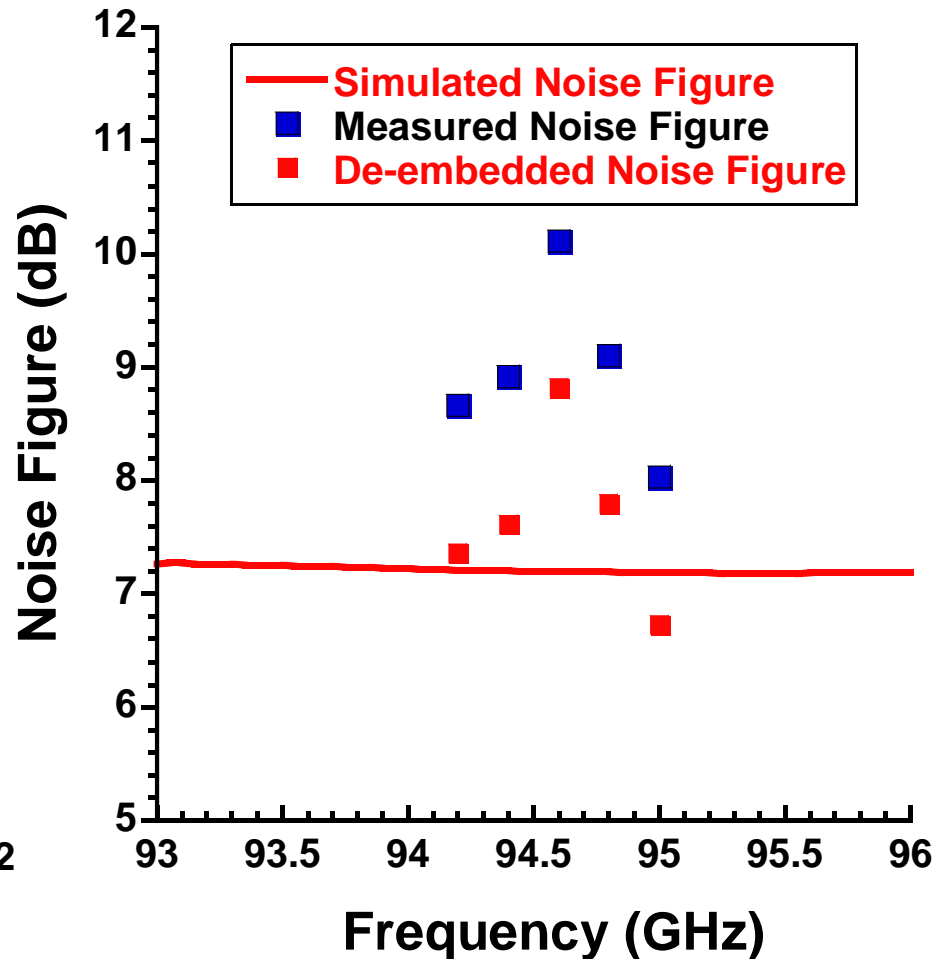
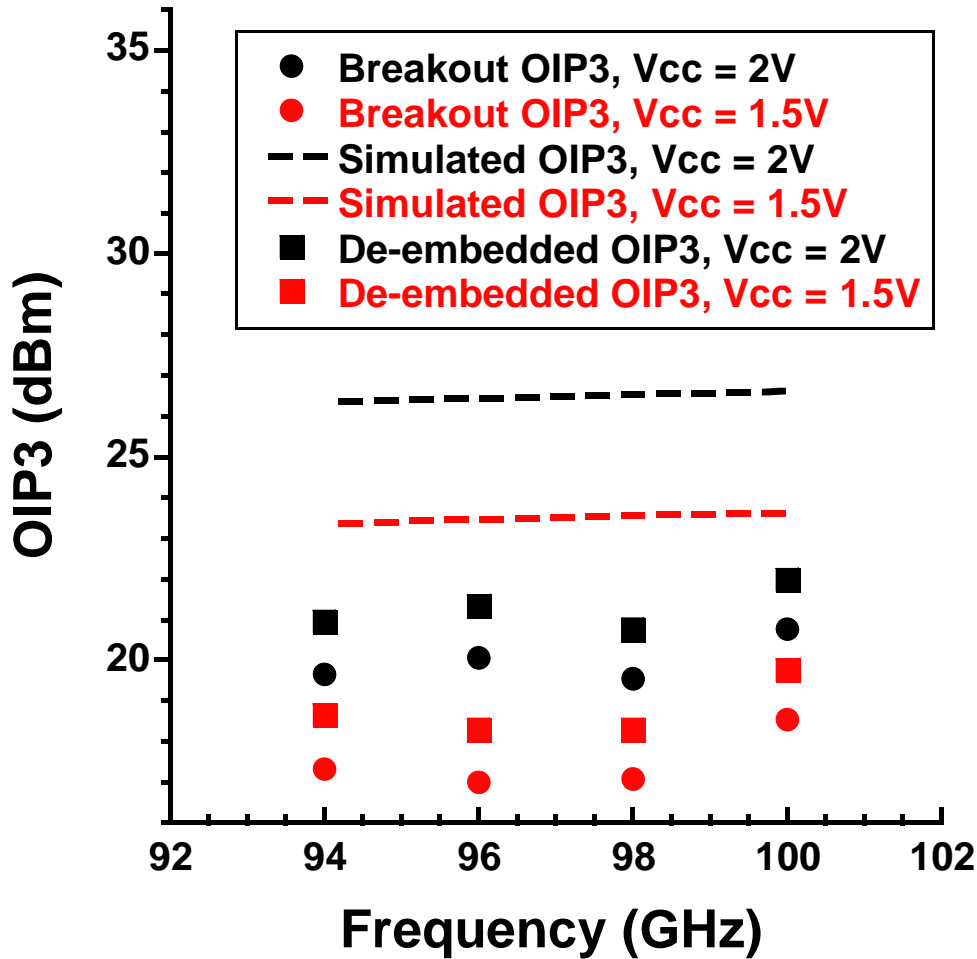
Low-gain (high-IIP3) design



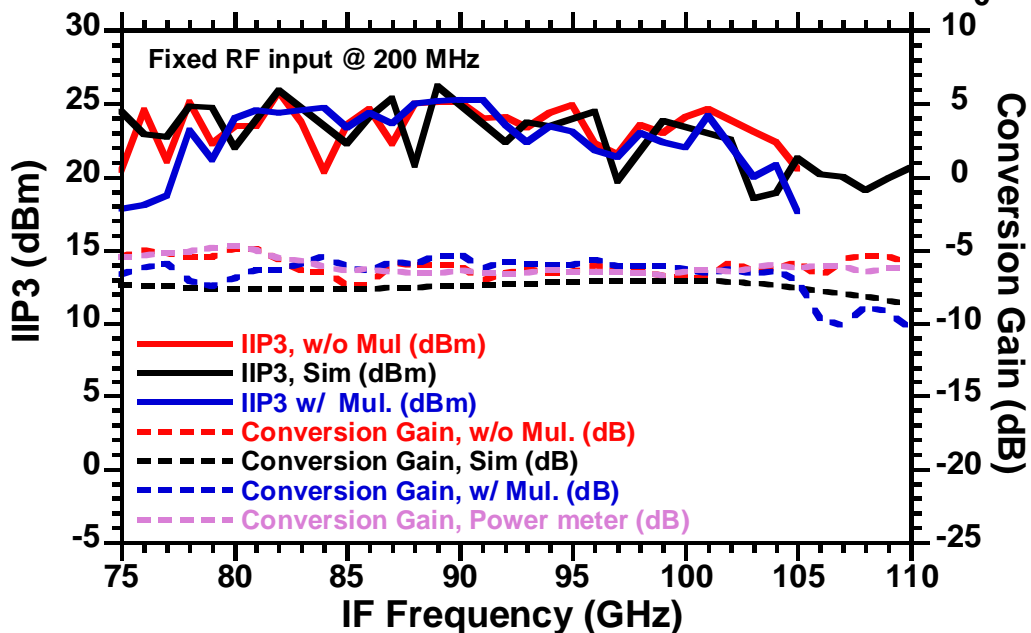
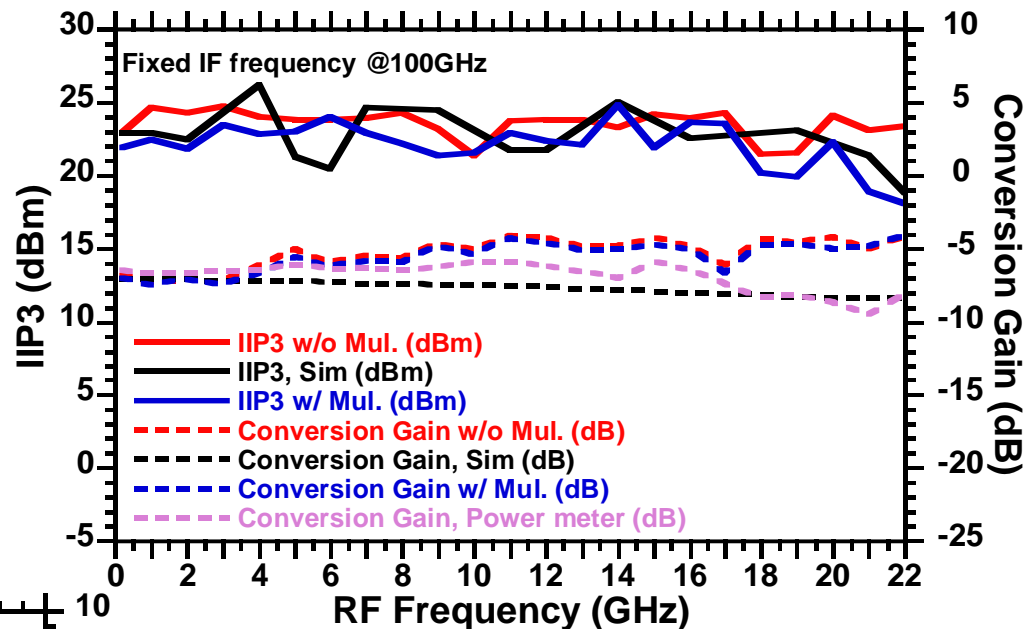
Power consumption: 97 mA @ 2 V
Peak gain: 5.9 dB @ 95 GHz, 5.7 dB @ 100 GHz



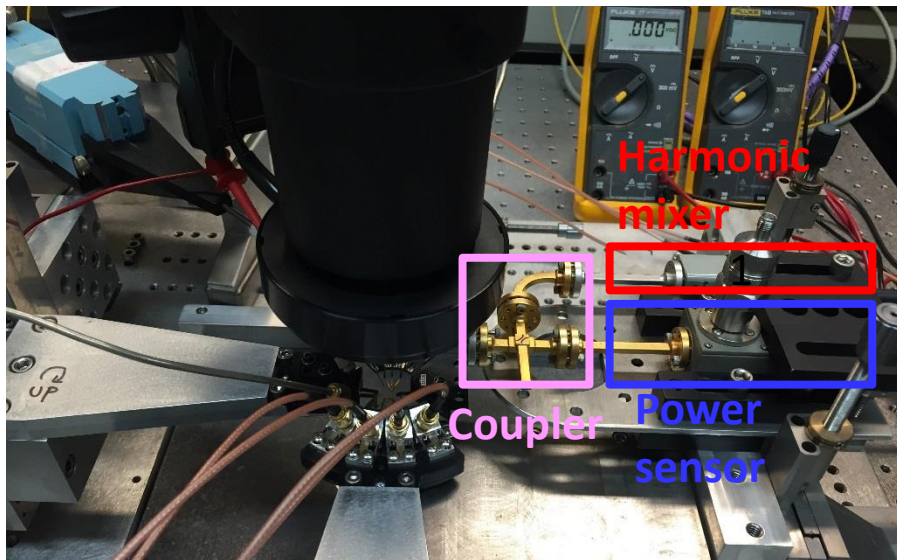
IF Amplifier measurement results



Performance: upconversion block



Upconversion measurement: Gain, IM3



Harmonic mixer

$$LO = (RF+IF)/n$$

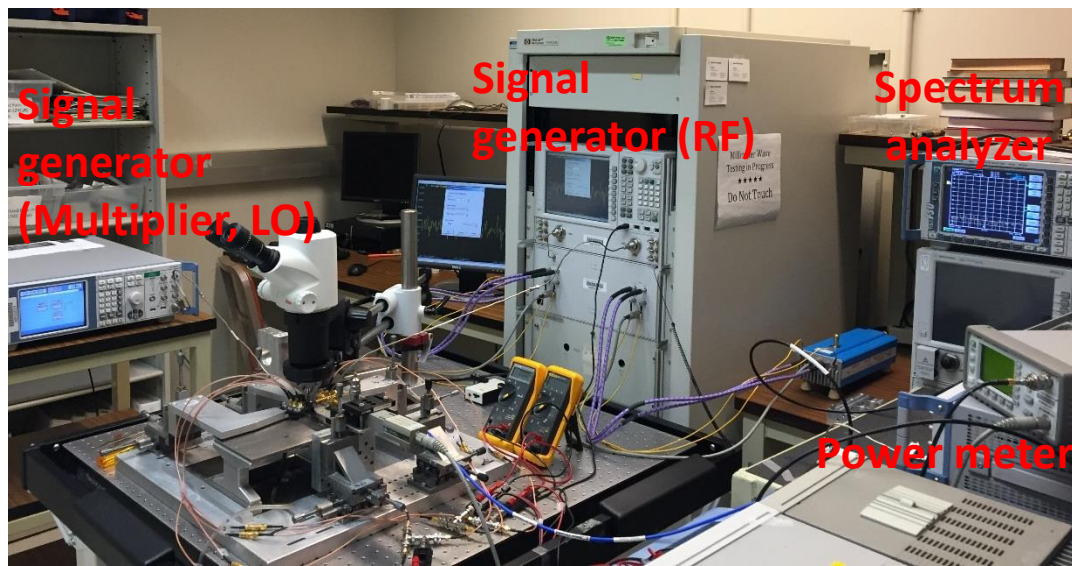
In our test:

$$n=10 \text{ and } IF = 1 \text{ GHz}$$

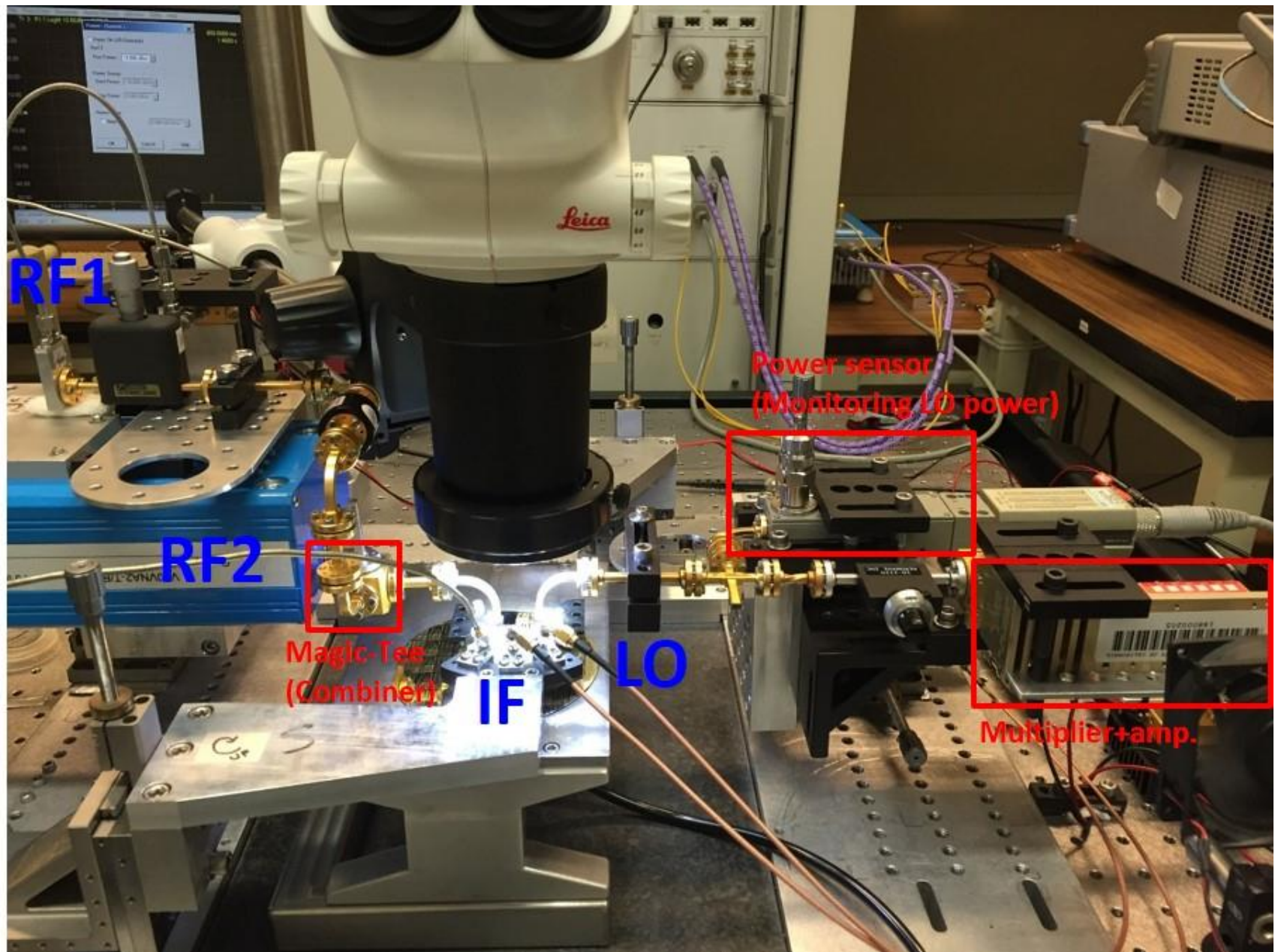
Frequency measurement: Harmonic mixer

Power measurement: power meter

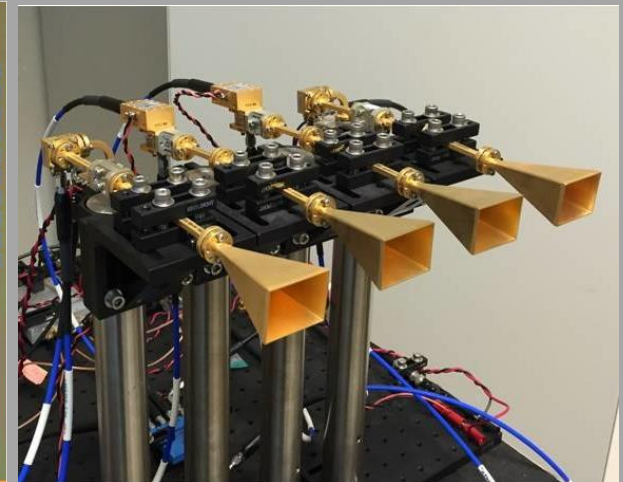
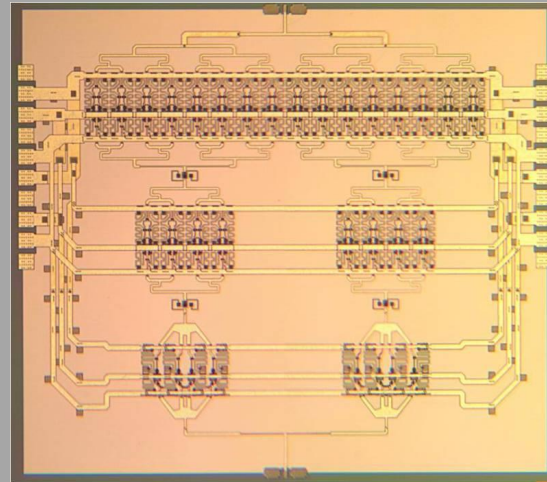
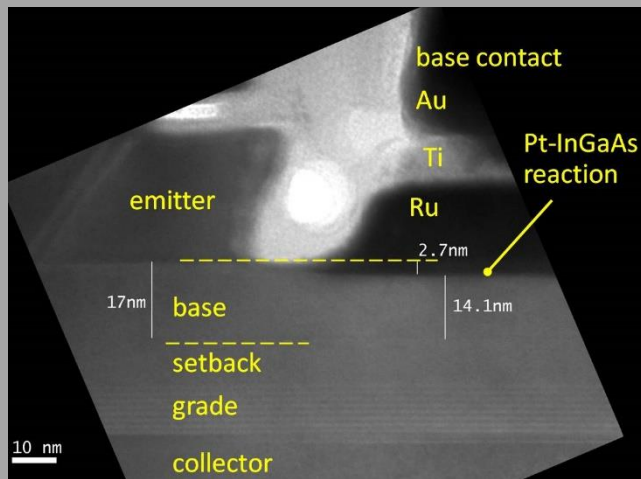
*Harmonic mixer LO frequency was adjusted to measure LO feedthrough (Harmonic mixer IF =1 GHz)



Downconversion measurement: IP3

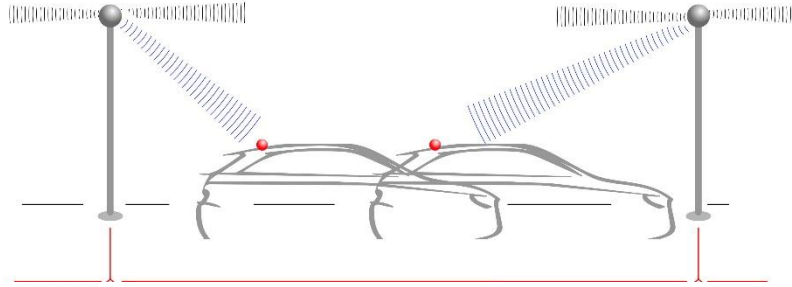
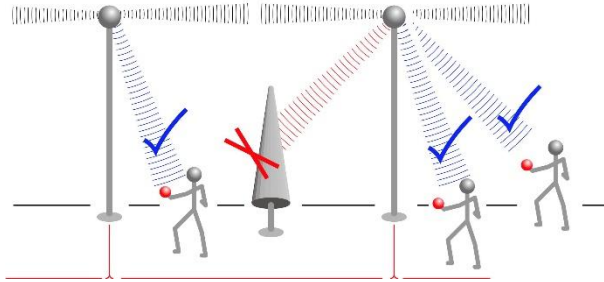


mm-Wave Wireless

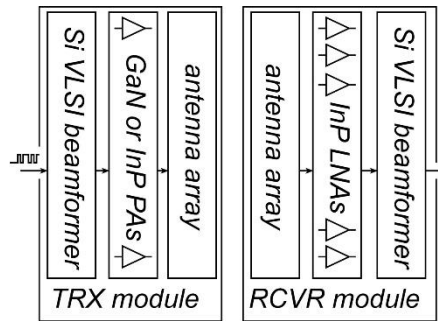
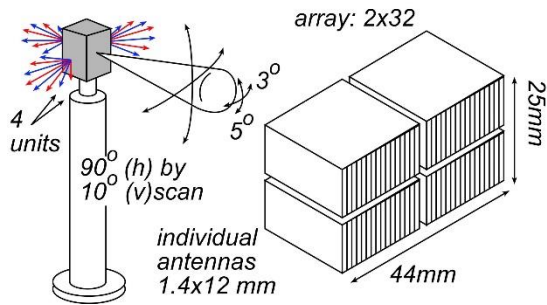


mm-Wave Wireless Electronics

Mobile communication @ 2Gb/s per user, 1 Tb/s per base station



Requires: large arrays, complex signal processing, high P_{out} , low F_{min}



**VLSI beamformers
VLSI equalizers
III-V LNAs & PAs (?)**

(backup slides follow)